AIR FORCE MATERIALS LABORATORY
AIR FORCE SYSTEMS COMMAND
Contract F33615-68-C-1225

# REFRACTIVE INDEX OF OPTICAL MATERIALS IN THE INFRARED REGION

AD704555

A. J. MOSES

DS-166
JANUARY 1970

Reproduced by the
CLEARINGHOUSE
for Federal Scientific & Technical
Information Springfield Va 22151

EPIC

ELECTRONIC
PROPERTIES
INFORMATION
CENTER

DDC
RECEIVED
APR 22 1970
C

HUGHES
HUGHES AIRCRAFT COMPANY
CULVER CITY CALIFORNIA

This document has been approved for public release and sale;
its distribution is unlimited.

249

# REFRACTIVE INDEX OF OPTICAL MATERIALS IN THE INFRARED REGION

A. J. MOSES

EPIC

ELECTRONIC
PROPERTIES
INFORMATION
CENTER

HUGHES

HUGHES AIRCRAFT COMPANY
CULVER CITY CALIFORNIA

## ABSTRACT

Refractive index data and some extinction coefficients are provided for the infrared region for the following materials: silicon, germanium, zinc sulfide, cadmium telluride, zinc selenide, silica, calcium fluoride, magnesium fluoride, aluminum oxide, magnesium oxide, aluminum, gold and silver. The dependence of these optical constants on wavelength, temperature, crystal form, film preparation technique, radiation and other factors is included.

This report has been reviewed and is approved for publication.


Sheldon J. Welles

Dr. Sheldon J. Welles, Head
Electronic Properties Information Center

E. F. Smith

E. F. Smith
Project Manager

TABLE OF CONTENTS


| | Page |
|---|---|
| FOREWORD | |
| INTRODUCTION | |
| ABSTRACT | |
| 1. TECHNICAL INTRODUCTION | 1-1 |
| General Information | 1-1 |
| Optical Spectrum | 1-1 |
| Materials Properties | 1-1 |
| 2. DEFINITIONS OF REFRACTIVE INDEX AND FACTORS AFFECTING THE REFRACTIVE INDEX | 2-1 |
| Definitions | 2-1 |
| Dependence on Wavelength | 2-2 |
| Dependence on Temperature | 2-2 |
| Dependence on Pressure | 2-4 |
| Dependence on Nuclear Radiation | 2-5 |
| Dependence on Materials Preparation Techniques | 2-6 |
| 3. METHODS FOR DETERMINING THE REFRACTIVE INDEX | 3-1 |
| Deviation | 3-1 |
| Reflection | 3-3 |
| Interference | 3-3 |
| Transmission | 3-5 |
| 4. PROBLEMS ASSOCIATED WITH FILMS | 4-1 |
| 5. REFRACTIVE INDEX DATA FOR SEMICONDUCTORS | 5-1 |
| Silicon | 5-5 |
| Introduction | 5-5 |
| Dependence on Wavelength | 5-8 |
| Dependence on Temperature | 5-17 |

TABLE OF CONTENTS (Continued)


| | Page |
|---|---|
| Dependence on Pressure | 5-22 |
| Dependence on Surface Condition | 5-23 |
| Germanium | 5-25 |
| Introduction | 5-25 |
| Dependence on Wavelength | 5-31 |
| Dependence on Temperature | 5-44 |
| Dependence on Pressure | 5-50 |
| Dependence on Film Thickness | 5-52 |
| Dependence on Film Composition | 5-53 |
| Dependence on Film Deposition Rate | 5-54 |
| Dependence on Film Deposition Atmosphere | 5-55 |
| Dependence on Film Deposition Substrate Temperature | 5-59 |
| Dependence on Electric Field | 5-61 |
| Zinc Sulfide | 5-63 |
| Introduction | 5-63 |
| Dependence on Wavelength | 5-65 |
| Cadmium Telluride | 5-75 |
| Introduction | 5-75 |
| Dependence on Wavelength | 5-78 |
| Dependence on Temperature | 5-90 |
| Zinc Selenide | 5-97 |
| Introduction | 5-97 |
| Dependence on Wavelength | 5-99 |
| Dependence on Temperature | 5-106 |

TABLE OF CONTENTS (Continued)


| | Page |
|---|---|
| 6. REFRACTIVE INDEX DATA FOR SILICA-QUARTZ-SILICON DIOXIDE | 6-1 |
| General | 6-1 |
| Silica, Crystalline | 6-3 |
| Introduction | 6-3 |
| Dependence on Wavelength | 6-5 |
| Silica, Fused | 6-15 |
| Introduction | 6-15 |
| Dependence on Wavelength | 6-17 |
| Dependence on Temperature | 6-28 |
| Dependence on Radiation | 6-30 |
| 7. REFRACTIVE INDEX DATA FOR FLUORIDES AND SELECTED CERAMICS | 7-1 |
| Calcium Fluoride | 7-3 |
| Introduction | 7-3 |
| Dependence on Wavelength | 7-5 |
| Dependence on Temperature | 7-13 |
| Magnesium Fluoride | 7-15 |
| Introduction | 7-15 |
| Dependence on Wavelength | 7-16 |
| Aluminum Oxide-Corundum-Sapphire-Ruby | 7-19 |
| Introduction | 7-19 |
| Dependence on Wavelength | 7-23 |
| Dependence on Temperature | 7-31 |

TABLE OF CONTENTS (Continued)


| | | Page |
|---|---|---|
| | Magnesium Oxide | 7-33 |
| | Introduction | 7-33 |
| | Dependence on Wavelength | 7-36 |
| | Dependence on Temperature | 7-43 |
| 8. | REFRACTIVE INDEX DATA FOR METALS | 8-1 |
| | Introduction | 8-1 |
| | Data Summary | 8-2 |
| | Aluminum | 8-5 |
| | Dependence on Wavelength | 8-5 |
| | Dependence on Temperature | 8-9 |
| | Gold | 8-11 |
| | Dependence on Wavelength | 8-11 |
| | Dependence on Temperature | 8-18 |
| | Dependence on Film Thickness | 8-19 |
| | Silver | 8-21 |
| | Dependence on Wavelength | 8-21 |
| | Dependence on Film Thickness | 8-28 |
| | Dependence on Temperature | 8-29 |
| 9. | BIBLIOGRAPHY | 9-1 |
| | EPIC-Indexed References | 9-1 |
| | Other References | 9-13 |

## FOREWORD

This report was prepared by Hughes Aircraft Company, Culver City, California, under Contract Number F33615-68-C-1225. The work was administered under the direction of the Air Force Materials Laboratory, Air Force Systems Command, Wright-Patterson Air Force Base, Ohio, with Mr. B. Emrich, Project Engineer.

The Electronic Properties Information Center (EPIC) is a designated Information Analysis Center of the Department of Defense authorized to provide information to the entire DOD community. The purpose of the Center is to provide a highly competent source of information and data on the electronic, optical and magnetic properties of materials of value to the Department of Defense. Its major function is to evaluate, compile and publish the experimental data from the world's unclassified literature concerned with the properties of materials. All materials relevant to the field of electronics are within the scope of EPIC: insulators, semiconductors, metals, super-conductors, ferrites, ferroelectrics, ferromagnetics, electroluminescents, thermionic emitters and optical materials. The Center's scope includes information on over 100 basic properties of materials; information generally regarded as being in the area of devices and/or circuitry is excluded.

The Center provides a technical answering service in which the technical staff responds to inquiries ranging in complexity from simple requests for data point values to requests for comprehensive reviews of the literature. This service is available to U. S. Government agencies, their contractors, subcontractors, suppliers, and those in a position to support the defense effort. Inquiries may be directed to:

Electronic Properties Information Center
Hughes Aircraft Company
Bldg. 6: E-175
Centinela and Teale Streets
Culver City, California 90230
Telephone: (213) 391-0711 Ext. 6596

The EPIC Bulletin, published quarterly, announces new publications and current activities of the Center. Users may request receipt of the Bulletin on a regular basis.

# INTRODUCTION

These data sheets have been prepared to meet a need for infrared refractive index information on optical materials with emphasis on high temperature utilization. Sources of information for these data sheets include periodicals, reports, proceedings of meetings and vendor literature. In addition to the 40,000 entries in the EPIC files, non-indexed material was also drawn upon to provide the desired degree of completeness. Inadequate materials characterization and differences in experimental techniques have made it unwise to judge the quality of the data and have resulted in a presentation of most of the data from the literature. In addition to the dependence of the refractive index and extinction coefficient on wavelength, the dependence on crystal form, film preparation techniques, temperature and radiation are considered. The designer will also find optical transmission plots and physical property information to be helpful.

The data sheets are organized in eight chapters comprising a technical introduction, definitions, experimental measurement techniques, problems associated with films, refractive index data for semiconductors, fluorides and ceramics, and metals. For convenience, a conversion table from wave number to wavelength is provided in the Appendix. The bibliography is divided into two parts where the first part lists references in the EPIC system, e.g., McCarthy (26010), and the second part lists non-EPIC references, e.g., Kodak[1967].

Users of the data sheets are encouraged to bring to the author's attention omissions of appropriate data so that supplements will be reasonably complete.

# CHAPTER 1
# TECHNICAL INTRODUCTION

## GENERAL INFORMATION

This report provides a concentration of data for optical constants of thirteen materials with emphasis on the refractive index in the infrared region of the optical spectrum. Considerable extinction coefficient data are also included as an aide to the design engineer. The refractive indices and extinction coefficients are presented as a function of (1) wavelength, (2) temperature, (3) pressure, (4) materials preparation technique and (5) radiation environment.

## OPTICAL SPECTRUM

The optical spectrum is illustrated in Figure 1-1. This report emphasizes the infrared region between 0.8 and 1000 microns, though some data for the ultraviolet and visible regions are included.

## MATERIALS PROPERTIES

Properties of optical materials are summarized in Table 1-1. This table includes some physical and mechanical properties in addition to optical data and crystal structures because it is realized that the selection of an optical material cannot be based on optical data alone. Transmittance data for the infrared region are included as additional reference material (Figures 1-2 to 1-10). By their nature, cubic crystals have isotropic properties and are therefore preferred for many optical applications. Non-cubic crystals divide incident light into two separate components which travel at different velocities and are consequently refracted to different degrees. This phenomenon is called "double refraction," or, "birefringence." However, crystals that are tetragonal, hexagonal and rhombohedral have one axis along which there is only single refraction. These systems have one optic axis and are called "uniaxial," whereas rhombic, monoclinic and triclinic crystals are biaxial. Crystal classes for optical materials are included in Table 1-1 and are illustrated in Figure 1-11.

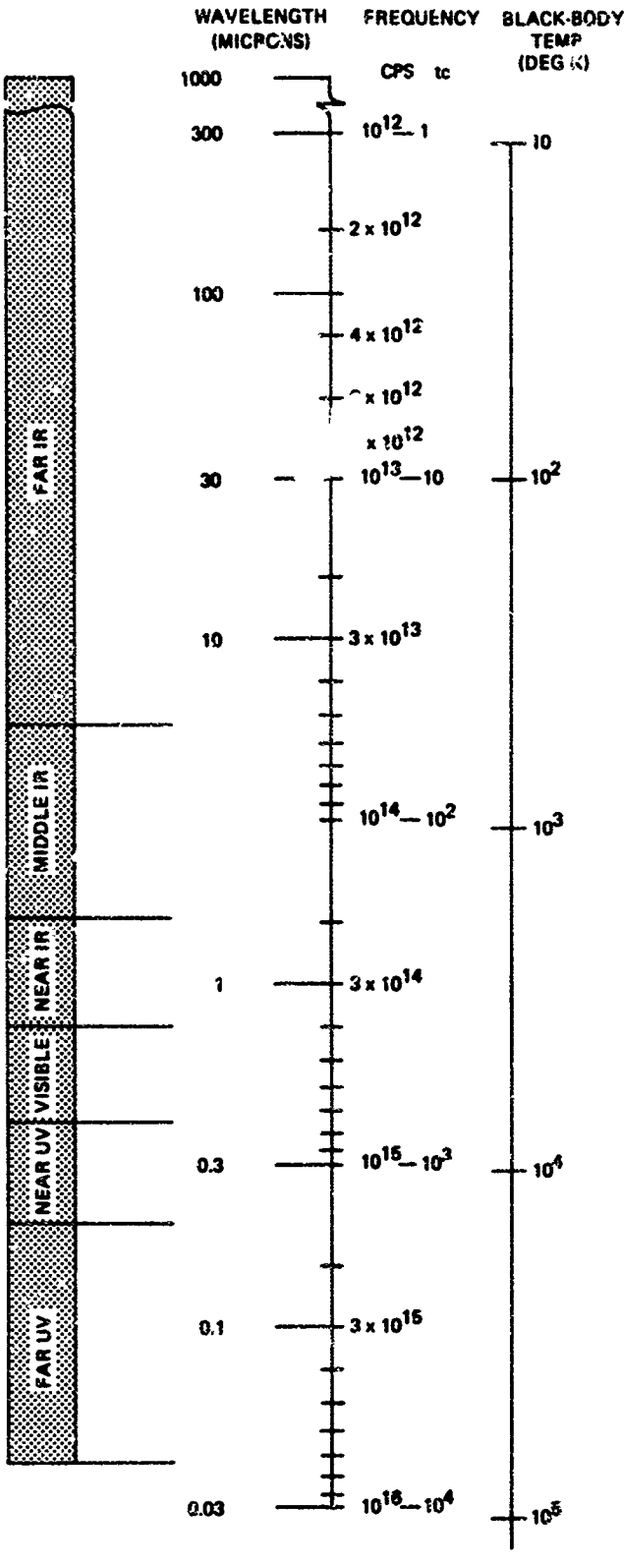



Figure 1-1. Optical Spectrum.

## Table 1-1. Properties of Materials for Infrared Optics*

| Material | Type of Crystal | Density (g/cm3) | Energy Gap (ev) at 298°K | Refractive Index at ~3μ and 298°K | Useful Upper Transmission limit (μ) (2 mm. thickness, 10% external transmittance) | Youngs' Modulus ($10^6$ p.s.i.) at 298°K | Hardness Knoop No. | Melting or Softening Point (°K) | Coefficient of Thermal Expansion ($10^{-6}$/°K) |
|---|---|---|---|---|---|---|---|---|---|
| Germanium | Cubic (diamond) | 5.33 | 0.8 | 4.037 | 23 | 14.9 | 700-880 | 1209 | 5.5 |
| Silica (crystal) | Hexagonal | 2.65 | | 1.499 | 4.5 | 12.6 | 741 | 1743 | 7.97, 13.37 |
| Silica (fused) | | 2.20 | | 1.419 | 4.5 | 10.6 | 461 | 1943 | 0.55 |
| Sapphire | Hexagonal | 3.98 | 7 | 1.702 | 6.5 | 50.0 | 1370 | 2303 | 6.7 |
| Silicon | Cubic (diamond) | 2.33 | 1.206 | 3.43 | 15 | 19.0 | 1100-1400 | 1693 | 4.7 |
| Aluminum | Face-centered cubic | 2.70 | | 3.90 | | $7.06 \times 10^5$ | 25 Brinell | 933 | 23.5 |
| Gold | Face-centered cubic | 19.32 | | 2.80 | | $7.8 \times 10^5$ | 28 Brinell | 1336 | 14.1 |
| Silver | Face-centered cubic | 10.5 | | 2.00 | | $8.27 \times 10^5$ | 91 Rockwell F | 1234 | 19.1 |
| Magnesium Fluoride | Tetragonal | 3.18 | | 1.364 | 9 | 16.6 | 576 | 1498 | 11.0 |
| Zinc Sulfide | α form hexagonal cubic | 4.09 | 5.4 | 2.256 | 14.5 | 14 | 354 | 1103 | 6.9 |
| Calcium Fluoride | cubic | 3.18 | | 1.418 | 11.5 | 14.5 | 158 | 1653 | 20.0 |
| Zinc Selenide | cubic | 5.27 | 4.68 | 2.440 | 22 | 10.3 | 150 | 1793 | 7.7 |
| Magnesium Oxide | cubic | 3.58 | 7.77 | 1.692 | 9.5 | 48.2 | 692 | 3073 | 12.0 |
| Cadmium Telluride | cubic | 5.85 | 1.58 | 2.695 | 31 | 5.3 | 45 | 1318 | 5.9 |

*Values may depend on selected crystal axis.

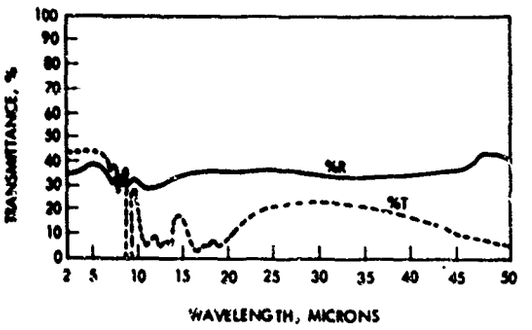



Figure 1-2. Silicon, 1 cm.

Ref. McCarthy (38757)

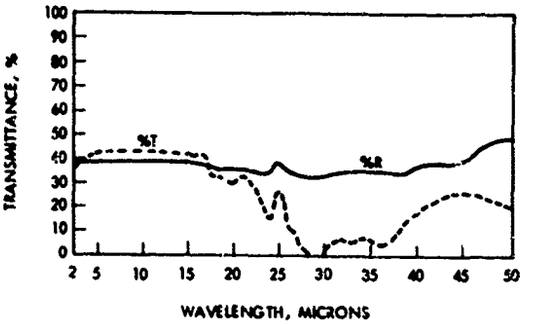



Figure 1-3. Germanium, 1.6 mm.

Ref. McCarthy (38757)

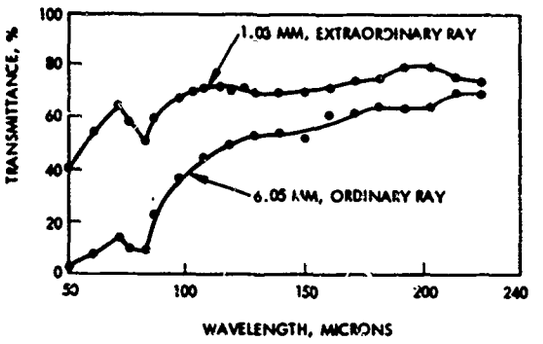



Figure 1-4. Transmission in Far Infrared by Crystalline Silica

Ref. Cartwright [1934]

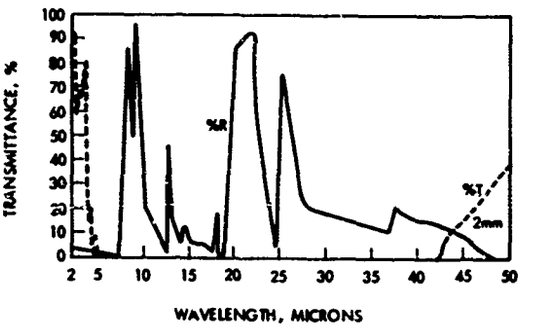



Figure 1-5. Fused Silica, 1 cm.

Ref. McCarthy (38757)

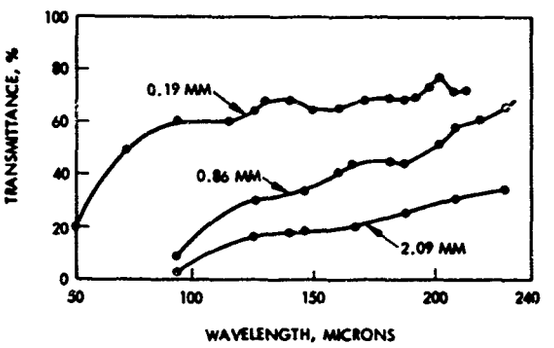



Figure 1-6. Transmission in Far Infrared by Fused Silica

Ref. Cartwright [1934]

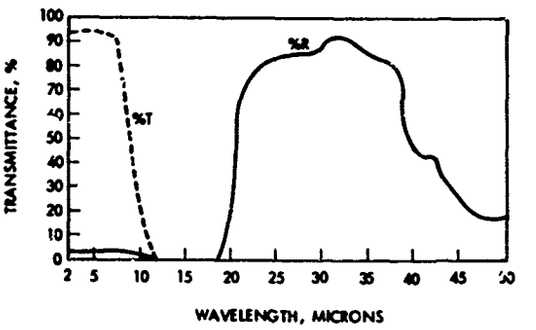



Figure 1-7. Calcium Fluoride, 5 mm.

Ref. McCarthy (38757)

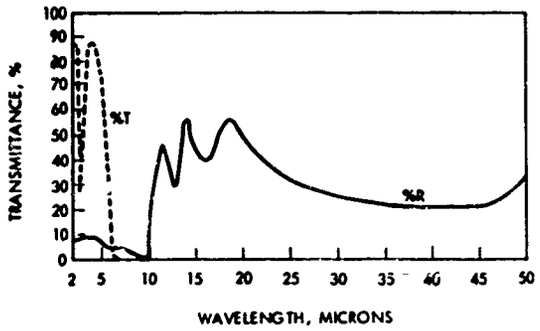



Figure 1-8. Aluminum Oxide – Sapphire, 2 mm.

Ref. McCarthy (26010)

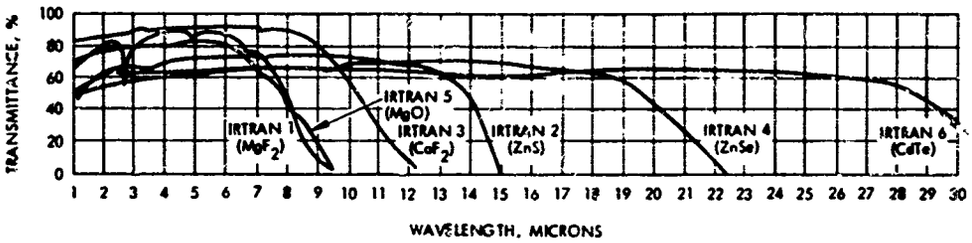



Figure 1-9. Transmission for 2mm Thick Polycrystalline Irtran Samples

Ref. Kodak [1967]

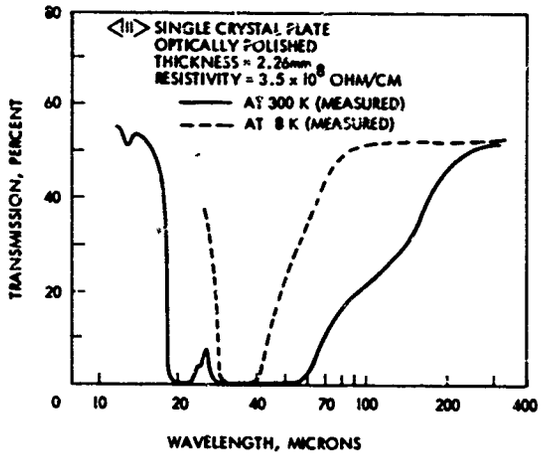



Figure 1-10. Far Infrared Transmission of high resistivity CdTe at 300 K and 8 K

Ref. Johnson, et al [40781]

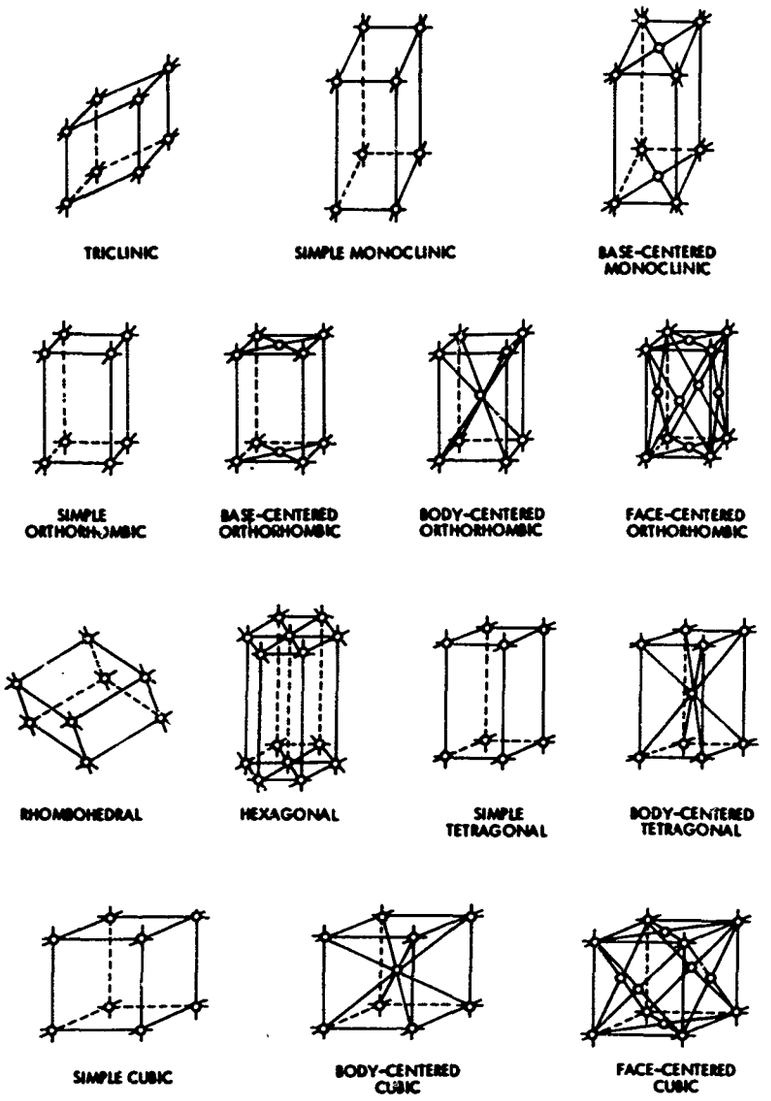



Figure 1-11. Crystal Systems.

## CHAPTER 2

## DEFINITIONS OF REFRACTIVE INDEX AND FACTORS AFFECTING THE REFRACTIVE INDEX

### DEFINITIONS

The refractive index (n) of a material is defined as the ratio of the phase velocity (c) of electromagnetic radiation in vacuum to the phase velocity (v) of the same radiation in the material, or:

$$n = c/v$$

However, since the index of refraction of air is only about 1.0003, it is frequently measured with respect to air instead of vacuum and no correction made for air.

In non-absorbing media, the refractive index is real, while in absorbing media a complex index of refraction (N) is sometimes used. The complex index of refraction is frequently defined as:

$$N = n + ik$$

where k = extinction coefficient or absorption index and $i = \sqrt{-1}$. Both n and k are frequency-dependent.

The real and imaginary parts of the square of the complex refractive index satisfy the <u>Kramers-Kronig relations</u>, as follows:

$$N^2 = (n + ik)^2 = (n^2 - k^2) + 2\,nki$$

$$n^2(\omega) - k^2(\omega) = \frac{2}{\pi} \int_0^\infty \frac{\omega' 2n(\omega')k(\omega')d\omega'}{\omega'^2 - \omega^2} + \text{constant}$$

$$2n(\omega)k(\omega) = \frac{-2\omega}{\pi} \int_0^\infty \frac{n^2(\omega') - k^2(\omega')\ d\omega'}{\omega'^2 - \omega^2}$$

This is, if the absorption index as a function of frequency is known, both $n(\omega)$ and $k(\omega)$ can be evaluated separately.

Optically anisotropic materials divide incident light into two components (double refraction) which are refracted along two mutually perpendicular planes. The ordinary wave travels at a velocity that is independent of the direction of propagation. The extraordinary wave travels at a velocity that is dependent on the relation between its direction and the optic axis. Single refraction occurs for light that travels parallel to the optic axis. The refractive index for the ordinary wave bears the symbol $n_o$, while $n_e$ denotes the extraordinary wave. Both $n_o$ and $n_e$ are dependent on frequency. Most types of crystals are anisotropic, giving rise to both $n_o$ and $n_e$. Cubic crystals have refractive indices that are identical in all directions (isotropic) for which reason they are often used in optical instruments.

In this compilation, emphasis is placed on the refractive index for the ordinary wave and for simplicity the corresponding refractive index is denoted by the symbol "n".

## DEPENDENCE ON WAVELENGTH

The refractive index of optical materials is dependent on the wavelength of the incident light, as shown for the ordinary refractive index of such materials in Figure 2-1. The refractive indices in Figure 2-1 range from about 1.3 to greater than 33, with glasses in the region between 1.3 and 2.0, semiconductors between 3.4 and 4.1, and metals as high as 33.

The slope of curves from Figure 2-2, $dn/d\lambda$, represents the dispersion and the wavelength-dependence of dispersion is evident from Figure 2-2.

## DEPENDENCE ON TEMPERATURE

The temperature coefficient of the refractive index is at least in part affected by the thermal expansion of the optical material, as shown by an approximate 10 percent contribution to the temperature coefficient of the refractive index for germanium [Ref. Cardona (2569).]

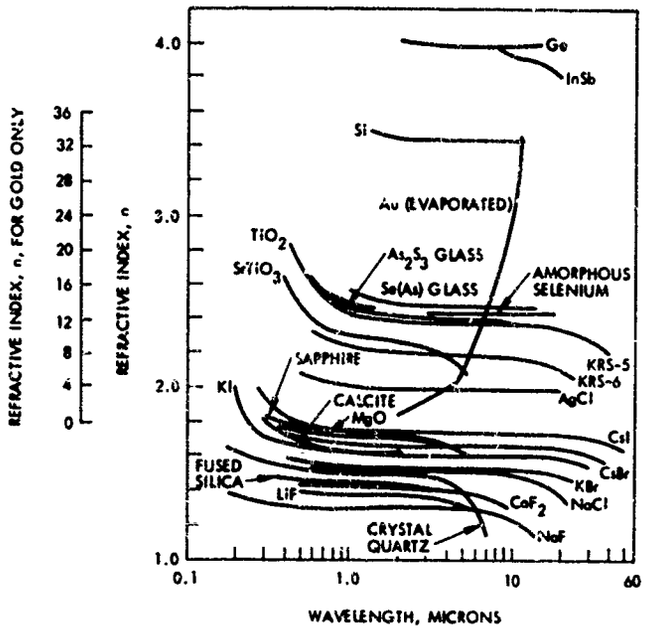



Figure 2-1. The refractive indices of selected optical materials.

Ref. Ballard (12539)

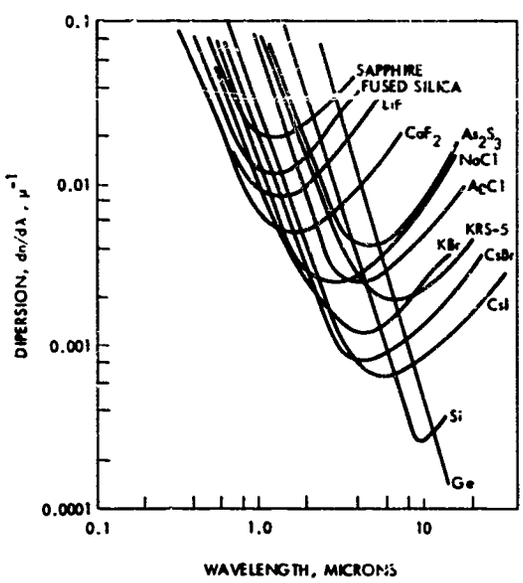



Figure 2-2. Dispersion for selected materials.

Ref. Wolfe [1965]

Heating a material causes a change in its dimensions. This change in dimensions is expressed by the linear coefficient of thermal expansion. In most cases, this coefficient is positive, increasing with rising temperature. The coefficient is usually small for optical materials, as may be seen from Table 1-1 and is wavelength-dependent (Figure 2-3). The occurrence of phase changes in the material can cause a major change in the coefficient of thermal expansion. For anisotropic crystals, the thermal expansion is also influenced by the direction of the heat flow. The correlation between refractive index, thermal change in refractive index, and linear thermal coefficient of thermal expansion for selected optical materials is demonstrated in Figure 2-4.

## DEPENDENCE ON PRESSURE

Application of external pressure on a material affects the material's refractive index in excess of changes attributable to compressibility and is explained by the existence of two effects due to pressure: (1) change in electron density and (2) change in electronic polarizability; the first effect produces an increase in refractive index with pressure, while the second effect reduces it. No wavelength-

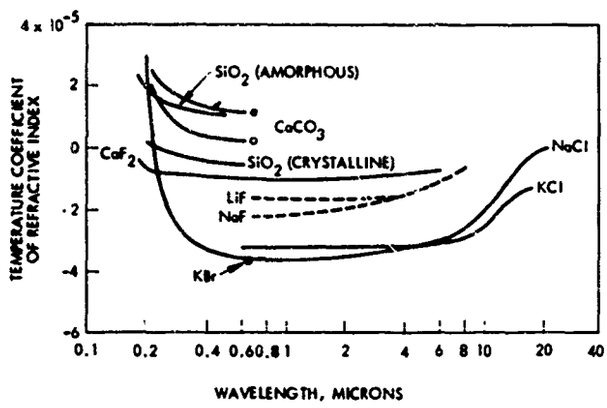



Figure 2-3. Temperature Coefficient of Refractive Index for Some Optical Materials

Ref. Smakula [1952]

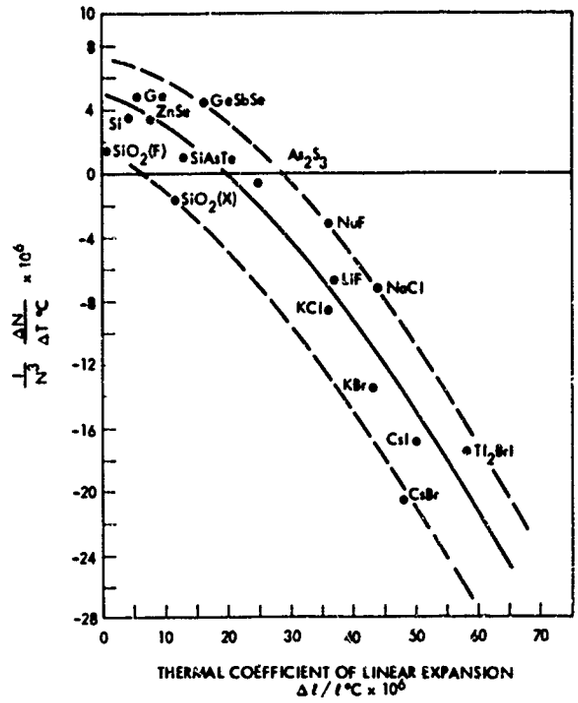



Figure 2-4. Correlation of refractive Index, Thermal Change in Refractive Index, and Linear Thermal Coefficient of Expansion for IR Optical Materials

Ref. Hilton Jones [1967]

dependence of the pressure coefficient of the refractive index is expected, at least in the near infrared region [(Ref. Cardona (2569)].

## DEPENDENCE ON NUCLEAR RADIATION

Nuclear radiation of space and laboratory origin can affect the refractive index of an optical material. Most of the studies involving radiation effects on the refractive index have been made on glasses. In this report, emphasis is placed on radiation effects to fused quartz since this material finds wide use on spacecraft as a window material.

## DEPENDENCE ON MATERIALS PREPARATION TECHNIQUE

The refractive index of a material is a function of the surface condition and chemical composition. In the case of evaporated films, the refractive index is also influenced by: evaporation atmosphere, substrate temperature, substrate material and orientation, condensation rate, film thickness and source temperature.

## CHAPTER 3
## METHODS FOR DETERMINING THE REFRACTIVE INDEX

Widely used methods for determining the refractive index of a material are based on the following principles:

1. Deviation
2. Reflection
3. Interference
4. Transmission

Fundamentals of these methods will be discussed in this chapter. Data tables in this report indicate which method was used to determine refractive indices.

### DEVIATION

Deviation methods, measuring the deviation of a beam of ligh. from a known path, can be considered to be the classical approach.

Deviation methods use a prism and therefore cannot be used for films. A typical deviation method is the prism deviation method, where the light is refracted through the prism at a given deviation which need not be the minimum deviation. Figure 3-1 illustrates the geometry of the prism, which permits calcuation of the refractive index as shown below. [Ref. Wolfe, et al (26316)].

$$\theta'_1 + \theta'_2 = \alpha$$

Snell's law provides the next pair of equations:

$$n_1 \sin \theta_1 = n_2 \sin \theta'_1$$

$$n_1 \sin \theta_2 = n_2 \sin \theta'_2$$

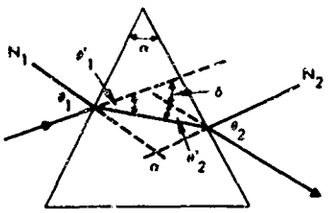



Figure 3-1. Prism Geometry for Minimum and Normal Deviation

Now a series of substitutions puts these equations in a form that simplifies solution of $n_2/n_1$:

$$n_1 \sin \theta_1 = n_2 \sin (\alpha - \theta'_2)$$

$$= n_2 (\sin \alpha \cos \theta'_2 - \cos \alpha \sin \theta'_2)$$

$$= n_2 \left[ \sin \alpha (1 - \sin^2 \theta'_2)^{1/2} - \cos \alpha \sin \theta'_2 \right]$$

$$\sin \theta'_2 = \frac{n_1}{n_2} \sin \theta_2$$

$$\sin \theta_1 = \sin \alpha \left[ (n_2/n_1)^2 - \sin^2 \theta_2 \right]^{1/2} - \cos \alpha \sin \theta_2$$

$$(n_2/n_1)^2 = \sin^2 \theta_2 + \frac{\sin^2 \theta_1 + 2 \sin \theta_1 \cos \alpha \sin \theta_2 + \cos^2 \alpha \sin \theta_2}{\sin^2 \alpha}$$

$$(n_2/n_1)^2 = \frac{\sin^2 \theta_2 + \sin^2 \theta_1 + \sin \theta_1 \cos \alpha \sin \theta_2}{\sin^2 \alpha}$$

$$n_2 = \frac{n_1}{\sin \alpha} (\sin^2 \theta_1 + \sin^2 \theta_2 + 2 \sin \theta_1 \sin \theta_2 \cos \alpha)^{1/2}$$

## REFLECTION

Reflection methods for determining optical constants are based on measurement of the reflection coefficient and the phase relationship between the two components of the reflected radiation, where one component is perpendicular to and the other component is parallel to the plane of incidence, as shown in Figure 3-2. In some reflection methods, both reflectivity and transmission must be measured but the data then permit the calculation of refractive index and extinction coefficient [Ref. Spitzer and Fan (791)].

A detailed description of a reflection method has been provided by Avery [Ref. Avery [1952]]. Avery's method briefly entails:

1. Determination of the ratio of the reflection coefficients ($\rho^2$) for incident light polarized in and perpendicular to the plane of incidence.
2. Let the complex refractive index be $N = n(1 - ik)$, then at the angle of incidence :

$$\rho^2 = \frac{a^2 + b^2 - 2a \sin\theta \tan\theta + \sin^2\theta\tan^2\theta}{a^2 + b^2 + 2a \sin\theta \tan\theta + \sin^2\theta\tan^2\theta}$$

where

$$N^2 - \sin^2\theta = (a - ib)^2$$

3. From curves relating $\rho^2$ to n and k for a number of angles of incidence, and measurements at two or more angles of incidence, n and k can be determined.

## INTERFERENCE

In principle, interferometric methods are based on dividing the light output of a source into two or more beams which are then superimposed. By illumination of parallel plates of a transparent material with these superimposed beams, reflection from the upper and lower

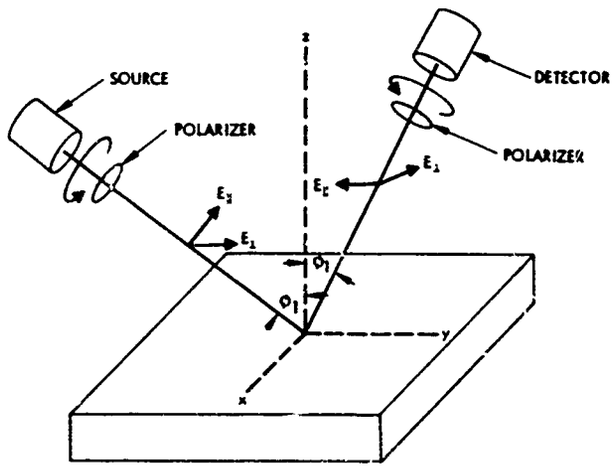



Figure 3-2. Geometry for the Reflection Method

Ref. Wolfe, et al, (26316)

surfaces will occur and an interference pattern will be created. [Ref. Wolfe, at al (26316)].

The Variable Angle Monochromatic Fringe observation (VAMFO) method represents an interferometric method for determining the thickness and refractive index of transparent films on reflective substrates using the apparatus depicted in Figure 3-3 [Ref. Pliskin & Fan (36787)]. The technique employs a rotating stage which is attached to an xy stage. Maxima and minima (fringes) are observed as the stage and samples are rotated, providing the number of fringes between angular limits. A microscope provides magnification. The refractive index is given by the equation.

$$n = \frac{\Delta m \lambda}{2t\,(\cos\theta_2 - \cos\theta_1)}$$

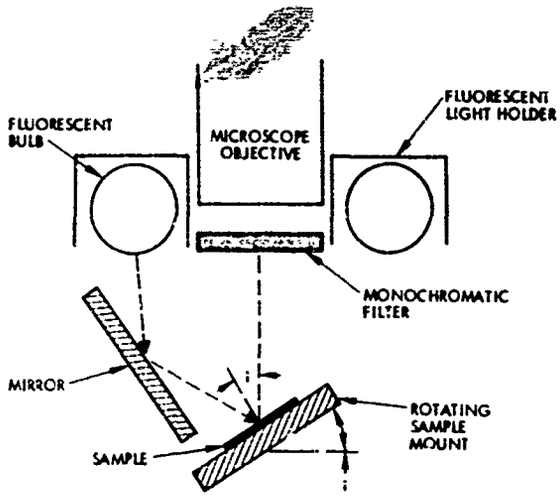



Figure 3-3. Diagram of VAMFO Apparatus

Ref. Pilskin and Fan (36787)

where

$\Delta m$ = number of fringes observed between refraction angles $\theta_1$ and $\theta_2$,

$t$ = film thickness

$\lambda$ = wavelength of filtered light

TRANSMISSION

The transmission method for determining the refractive index of films is based on the following equations:

$$2nt = m\lambda \text{ for maximum transmission}$$

and

$$2nt = (m + \frac{1}{2})\lambda \text{ for minimum transmission,}$$

where

$t$ = film thickness

$\lambda$ = wavelength of incident light

$m$ = the order number

The order number can be determined by using the first equation in the region of minimum dispersion, where the order number is low and the product 2nt is essentially constant. The film thickness is measured by other tests. [Ref. Wales, et al., (31497)].

# CHAPTER 4
# PROBLEMS ASSOCIATED WITH FILMS

The optical characteristics of films are sensitive to the film microstructure, which in turn is affected by various deposition parameters. The formed film is subject to aging effects including oxidation, recrystallization, hydrolysis, thermal decomposition, chemical reactions with the environment, and other causes. As a result of these factors, optical data for films often show a wide spread in values between observers.

Optical films are most commonly deposited by thermal evaporation in a vacuum onto a substrate that may be heated. Factors influencing the optical characteristics of evaporated films include the following:

1. Condensation rate
2. Source temperature
3. Substrate material
4. Substrate temperature
5. Ambient pressure
6. Nature of ambient environment
7. Film thickness.

Specific results showing the effects of these factors on the refractive index are presented on appropriate materials data sheets in this report. Some additional remarks relating to these factors serve to demonstrate the strong influence of some of the factors.

The presence of hydroxyl groups, usually formed by the reaction of water vapor with the material, causes an absorption band near 2.7 microns and a low refractive index at that wavelength. This phenomenon is most marked in sputtered, anodized, and electrodeposited films.

An example of aging is the growth of natural oxide on aluminum, which has been reported to reach a maximum thickness of 45 Angstroms in one month. Oxides usually have a different refractive index from that of the matrix, as is illustrated in Table 4-1, where germanium, silicon, aluminum and their oxides are compared.

Table 4-1. Comparison of Refractive Indices of Elements and Oxides

| Material | Wavelength, (microns) | Refractive Index (n) |
|---|---|---|
| Germanium | not stated | 4.0 |
| Germanium Oxide ($GeO_2$) | | |
| (hexagonal) | not stated | 1.735 |
| (tetragonal) | not stated | 2.05 - 2.10 |
| Silicon | 0.55 | 0.055 |
| Silicon monoxide (SiO) | 0.55 | 1.9 - 2.0 |
| Silicon sesquioxide ($Si_2O_3$) | 0.55 | 1.52 - 1.55 |
| Silicon dioxide | 0.55 | 1.46 - 1.47 |
| Aluminum | 2.0 | 2.3 |
| Aluminum oxide ($Al_2O_3$) | 2.0 | 1.74 |

The effect of surface oxide in metal deposition is particularly apparent where extremely thin films are laid down. Such ultra-thin films may act as getters for oxygen and other gases. On the other hand, the reducing property of a hydrogen atmosphere during evaporation can lead to a refractive index, representative of the pure element (e.g., germanium) because the hydrogen ties down the oxygen chemically. High substrate temperatures can cause a large reduction in refractive index by formation of a relatively thick oxide layer, as was demonstrated for germium by Davey, et al. [Ref. Davey at al., (13363)]. Even this short discussion of problems associated with films should convince the reader that published optical data for films should be used with caution.

# CHAPTER 5
# REFRACTIVE INDEX DATA FOR SEMICONDUCTORS

Electrons in crystals are located within energy bands, shown in Figure 5-1, and the bands are separated by regions for which no electron energy states are permitted; these regions are called "band gaps" or "energy gaps." In conductors, one or more of the bands are partially filled. In semiconductors, all bands are completely filled, except for one or two partially filled bands. Insulators possess allowed energy bands that are either empty or filled with no electrons available for movement in an electric field.

The distinction among conductors, semiconductors and insulators is of course not as sharply drawn as the preceding discussion might imply. Electrical resistivity measurements, summarized in Figure 5-2, show the wide range in resistivity between good conductors and good insulators. Figure 5-2 also shows the wide range within a class (e.g., insulators) and the effect of impurities on the electrical resistivity of semiconductors (germanium).

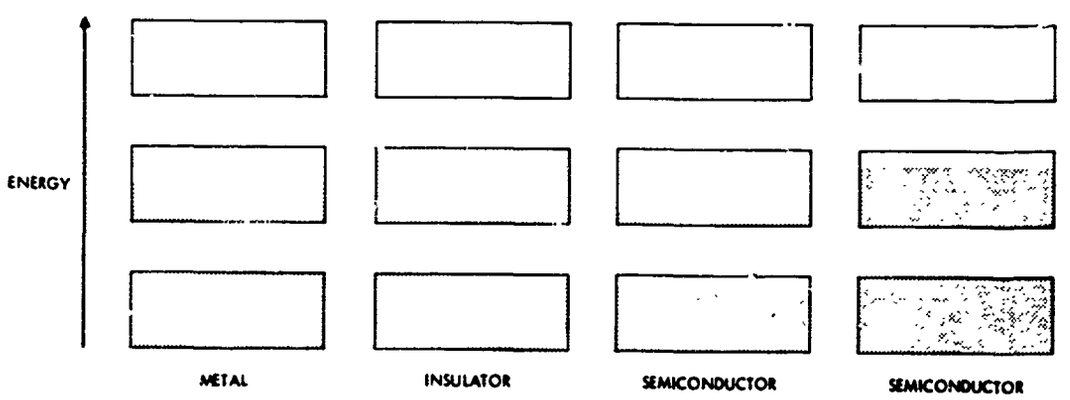



Figure 5-1. Schematic Electron Occupancy of Allowed Energy Bands for an Insulator, Metal, and Two Semiconductors. The Vertical Extent of the Boxes Indicates the Allowed Energy Regions; The Shaded Areas Indicate the Region Filled With Electrons

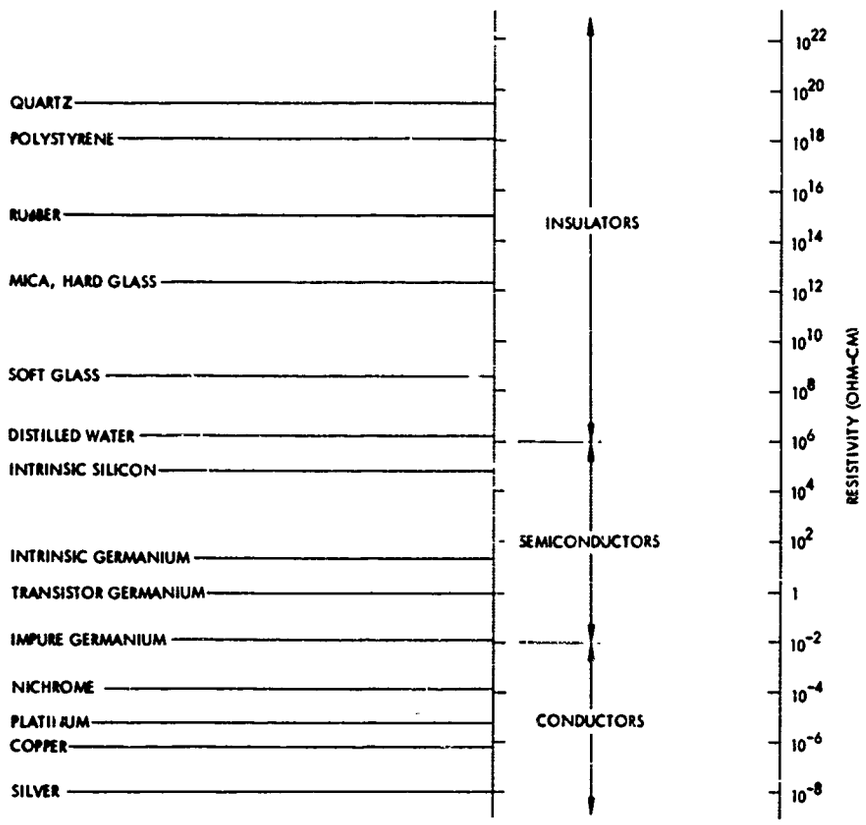



Figure 5-2. Electrical Resistivity of Materials

# SILICON

## INTRODUCTION

Silicon is a semiconductor that has found application in infrared optics, transistors, diodes, rectifiers, solar cells, alloys and as deoxidizer in steels. Silicon is the second most abundant element, usually occurring as oxide or silicate. Recovery from the oxide is accomplished by reduction with carbon. Purification is accomplished by distillation of silicon tetrachloride with subsequent reduction of the tetrachloride with zinc. Zone melting with solidification and growth of single crystals from the molten state provide further purification. Highly purified silicon has a resistivity of approximately $2.5 \times 10^5$ ohm-cm.

The physical properties of intrinsic silicon were summarized in Table 1-1. Impurities in silicon have an effect on a number of properties including electrical resistivity and optical transmission. It is therefore important to realize that differences in optical data of several authors may arise from different doping level; frequently, doping levels are not stated in publications. Doping levels are often expressed in terms of room temperature resistivity and Figure 5-3 provides the correlation between electrical resistivity and impurity concentration at 300°K. The optical transmission of silicon is summarized in Figure 1-2.

## DATA

All data presentations for silicon are listed in Table 5-1 and a summary of wavelength and temperature coverage is plotted in Figure 5-4. Most data for bulk silicon are believed to have been obtained from single crystal material, but experimenters have frequently failed to state the crystalline status of their specimens. Figures 5-5 to 5-14 and Tables 5-2 to 5-4 present refractive index data for bulk silicon for wavelengths from the visible region to 200 microns; Figure 5-15 shows the extinction coefficient for bulk silicon from 1.0 to 15 microns. The effect of the type of detector on the measured refractive index is evident from Figure 5-9. Figures 5-10 to 5-15 show data for doped specimens. Figures 5-14 and 5-15 present the optical properties of a highly doped

p-type surface on an n-type substrate, where the doped layer is considered to be semi-infinite; the effect of surface condition on the refractive index is also apparent from these Figures (see also Figures 5-23 and 5-29). Finally, Figure 5-16 shows the influence of wavelength on the refractive index of a silicon film. The effect of temperature on the refractive index is the subject of Figures 5-17 to 5-26 for temperatures between 77 and 960°K.

Intrinsic silicon shows good agreement in refractive index data and no large difference in refractive index is observable between bulk and films. No significant difference is detected between intrinsic bulk, single crystal and polycrystalline refractive indices. Doped materials do not exhibit a significant correlation between type and degree of doping, and refractive index.

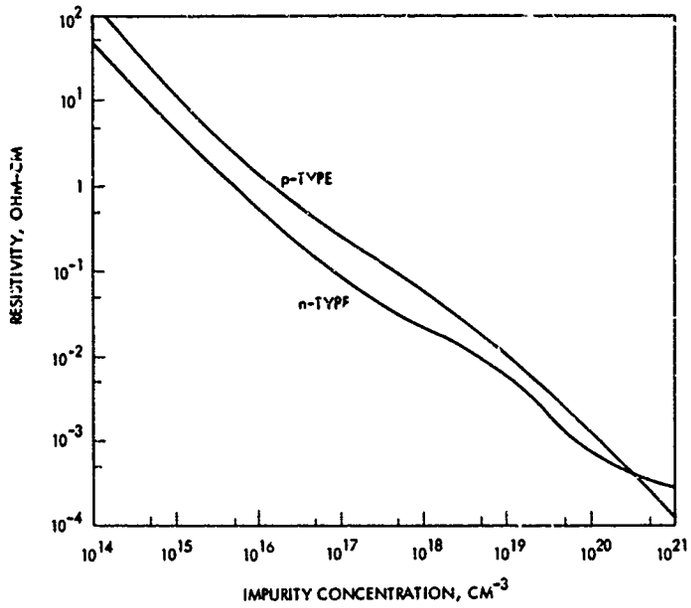



Figure 5-3. Resistivity at 300°K versus Impurity Concentration in Silicon [Irvin, (5250)]

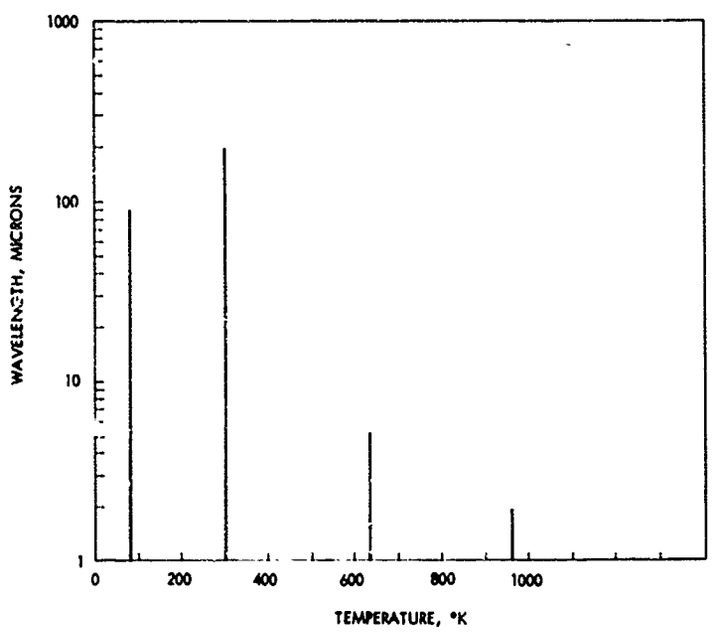



Figure 5-4. Wavelength and Temperature Range of Silicon Data

## Table 5-1. List of Silicon Data

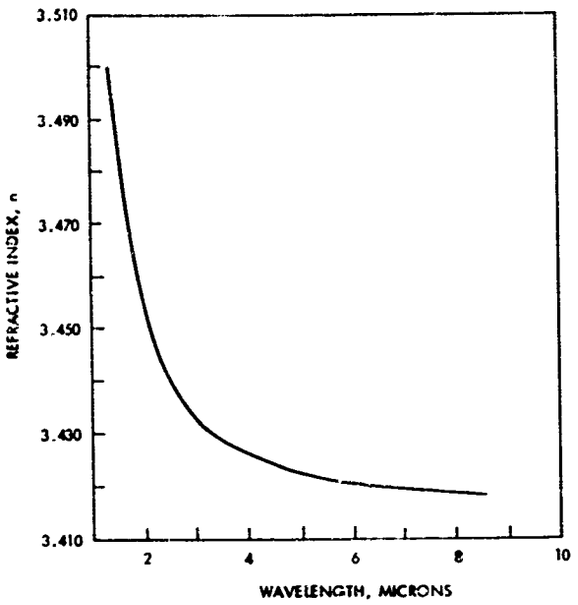
| Figure | Table | n or k | Form | Crystal | Wavelength Range (microns) From | To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-5 | 5-2 | n | Bulk | * | 1.4 | 11 | | Wavelength |
| 5-6 | | n | Bulk | Single | 0.1 | 5 | | Wavelength |
| | 5-3 | n | Bulk | Single | 26 | 200 | | Wavelength |
| 5-7 | | n | Bulk | Single | 1.1 | 4.8 | | Wavelength |
| 5-8 | | n | Bulk | * | 0.1 | 5 | 100, 297°K | Wavelength |
| 5-9 | | n | Bulk | * | 0.03 | 12 | | Wavelength |
| | 5-4 | n | Bulk | * | 1.0 | 2.6 | 85, 300°K | Wavelength |
| 5-10 | | n | Bulk | * | 25 | 180 | n-type | Wavelength |
| 5-11 | | n | Bulk | * | 25 | 180 | p-type | Wavelength |
| 5-12 | | n | Bulk | Poly | 4 | 12 | | Wavelength |
| 5-13 | | n | Bulk | * | 3.5 | 8.5 | vac. treated | Wavelength |
| 5-14 | | n | Bulk | * | 1 | 15 | p-type | Wavelength |
| 5-15 | | k | Bulk | * | 1 | 15 | p-type | Wavelength |
| 5-16 | | n | Film | Poly | 0.55 | 2.2 | | Wavelength |
| 5-17 | | dn/dT | Bulk | Single | 1.3 | 1.6 | p-type, 109-750°K | Temperature |
| 5-18 | | Δn | Bulk | * | 1.0 | 4.5 | | Temperature |
| 5-19 | | Δn/n | Bulk, Film | Single, * | 3.0 | 3.0 | 77-400°K | Temperature |
| 5-20 | | n | Bulk | * | 1.1 | 4.8 | 100-297 | Temperature |
| 5-21 | | n | Bulk | * | 1.3 | 5.2 | p-type, 109-750°K | Temperature |
| 5-22 | | n | Bulk | * | 0.9 | 2.0 | p-type, 280-960°K | Temperature |
| 5-23 | | n | Bulk | * | 25 | 180 | n-type, 85-300°K | Temperature |
| 5-24 | | n | Bulk | * | 0.1 | 5.0 | 100 - 297°K | Temperature |
| 5-25 | | n | Bulk | * | 0.9 | 2.0 | n-type, 280-960°K | Temperature |
| 5-26 | | dn/dT | Bulk | * | 0.45 | 2.0 | n-type, 280-960°K | Temperature |
| 5-27 | | n | Bulk | * | 0.1 | 5.0 | | Pressure |
| 5-28 | | n | Bulk | * | 1 | 15 | p-type | Surface |
| 5-29 | | k | Bulk | * | 1 | 15 | p-type | Surface |

*Not stated.

PRECEDING PAGE BLANK

**PARAMETER:** Wavelength

**MATERIAL:** Silicon




**FORM** Bulk mm

**THICKNESS** NA (Prism)

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.4-11 μ

**TEMPERATURE** 299 °K

**METHOD** Deviation

**REFERENCE** Salzberg & Villa (3900)

**REMARKS**

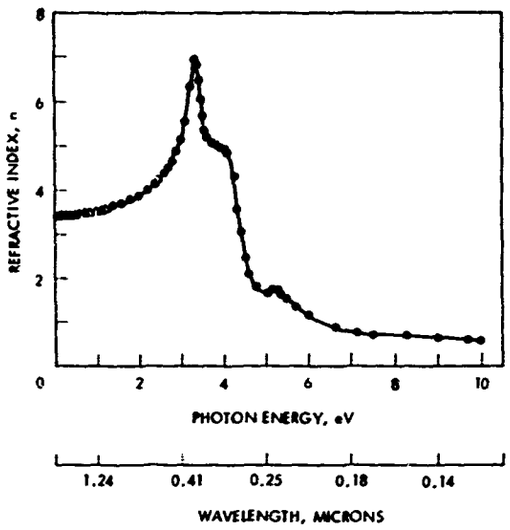
Figure 5-5

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 1.3570 | 3.4975 |
| 1.3673 | 3.4962 |
| 1.3951 | 3.4929 |
| 1.5295 | 3.4795 |
| 1.6606 | 3.4696 |
| 1.7092 | 3.4664 |
| 1.8131 | 3.4608 |
| 1.9701 | 3.4537 |
| 2.1526 | 3.4476 |
| 2.3254 | 3.4430 |
| 2.4373 | 3.4408 |
| 2.7144 | 3.4358 |
| 3.00 | 3.4320 |
| 3.3033 | 3.4297 |
| 3.4198 | 3.4286 |
| 3.50 | 3.4284 |
| 4.00 | 3.4255 |
| 4.258 | 3.4242 |
| 4.50 | 3.4236 |
| 5.00 | 3.4223 |
| 5.50 | 3.4213 |
| 6.00 | 3.4202 |
| 6.50 | 3.4195 |
| 7.00 | 3.4189 |
| 7.50 | 3.4186 |
| 8.00 | 3.4184 |
| 8.50 | 3.4182 |
| 10.00 | 3.4179 |
| 10.50 | 3.4178 |
| 11.04 | 3.4176 |

Table 5-2

PARAMETER: Wavelength

MATERIAL: Silicon




FORM Bulk, Single Crystal

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.1 - 5 μ

TEMPERATURE 300 °K

METHOD Reflection

REFERENCE Philipp & Taft (5951)

REMARKS Values above 1.0 micron were taken from Salzberg & Villa (3900).

Figure 5-6

| Wavelength (Microns) | Refractive Index, n |
|---|---|
| 26 - 29 | 3.41 ± 0.03 |
| 111-200 | 3.41 ± 0.03 |

THICKNESS 0.5 - 2.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 26-200 μ

TEMPERATURE 297 °K

METHOD Interference

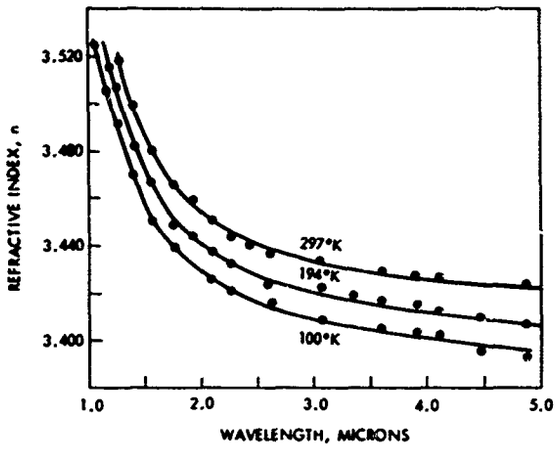
REFERENCE Aronson, et al. (16091)

REMARKS Crystal cut perpendicular to the [111] axis.

Table 5-3

**PARAMETER:** Wavelength

**MATERIAL:** Silicon




Published with permission
Copyright © 1959 Pergamon Press

**FORM** Single Crystal Prism

**THICKNESS** NA mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.1-4.8 μ

**TEMPERATURE** 100-297 °K

**METHOD** Deviation

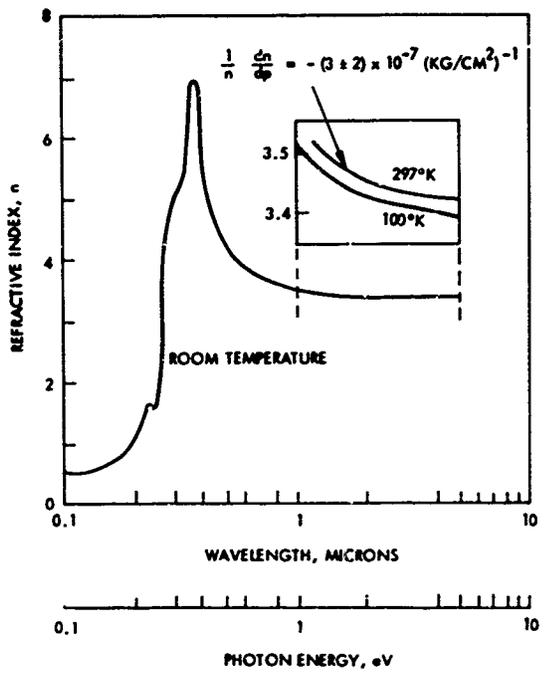
**REFERENCE** Cardona, et al. (620)

**REMARKS**

Figure 5-7

**PARAMETER:** Wavelength

**MATERIAL:** Silicon




**FORM** Bulk mm

**THICKNESS** not stated

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.1-5 μ

**TEMPERATURE** 100, 297 °K

**METHOD** not stated

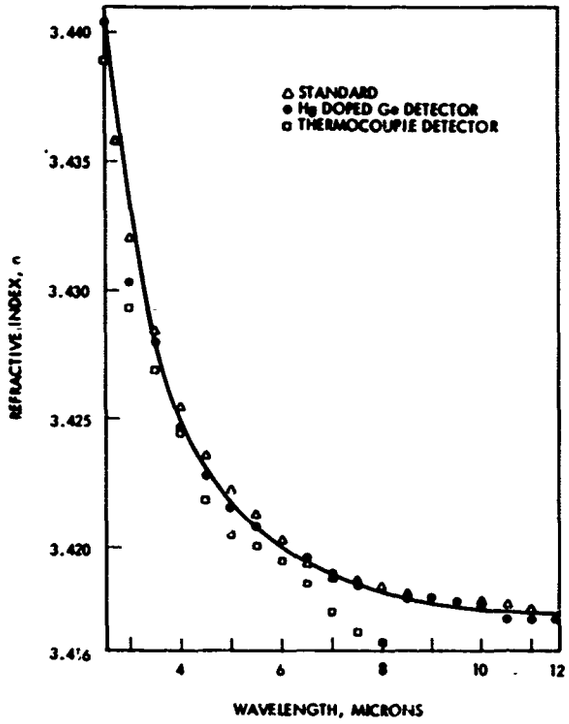
**REFERENCE** Evans (26567)

**REMARKS**

Figure 5-8

**PARAMETER:** Wavelength

**MATERIAL:** Silicon




**FORM** Bulk

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.03-12 μ

**TEMPERATURE** ~298 °K

**METHOD** Deviation

**REFERENCE** Hilton, et al., (25628)

**REMARKS**

Figure 5-9

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 1.05 | 3.565 |
| 1.10 | 3.553 |
| 1.20 | 3.531 |
| 1.40 | 3.499 |
| 1.60 | 3.480 |
| 1.80 | 3.466 |
| 2.00 | 3.458 |
| 2.20 | 3.451 |
| 2.40 | 3.447 |
| 2.60 | 3.443 |

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.0-2.6 μ

**TEMPERATURE** ~298 °K

**METHOD** Deviation

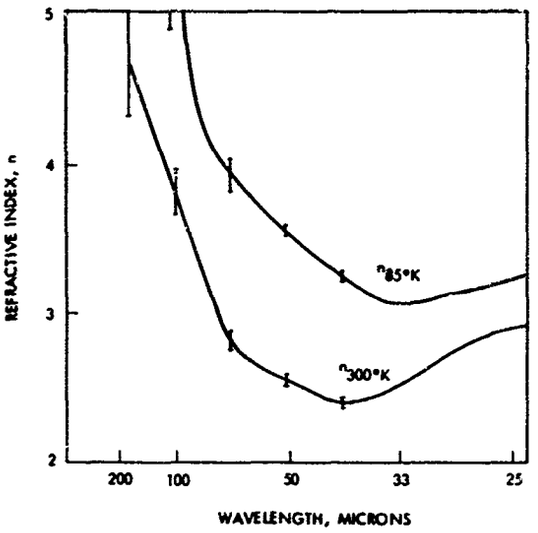
**REFERENCE** Briggs (13314)

**REMARKS**

Table 5-4

PARAMETER: Wavelength

MATERIAL: Silicon




FORM Bulk

THICKNESS 0.010 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 25-180 μ

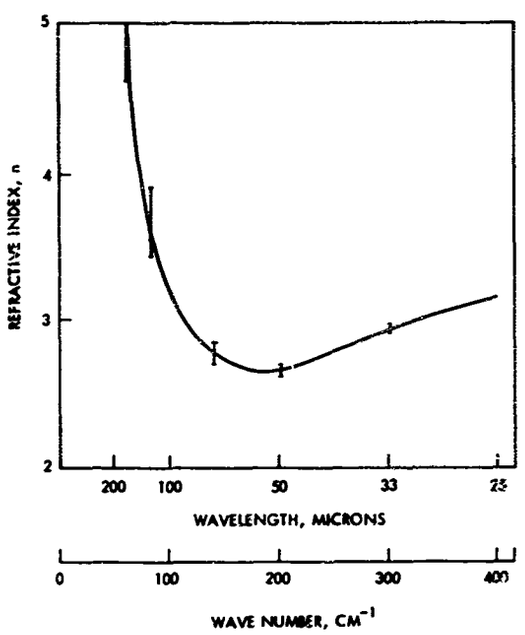
TEMPERATURE 85, 300 °K

METHOD Reflection

REFERENCE Balkanski & Besson (22653)

REMARKS Phosphorus-doped n-type silicon at concentration of $2.9 \times 10^{17}$ $cm^{-3}$ at 300°K.

Figure 5-10




THICKNESS 0.010 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 25-180 μ

TEMPERATURE 300 °K

METHOD Reflection

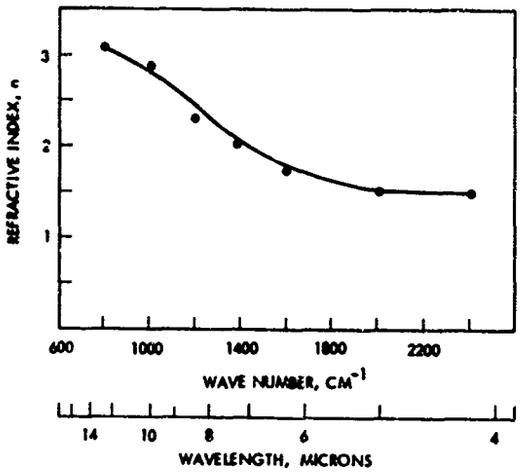
REFERENCE Balkanski & Besson (22653)

REMARKS Arsenic-doped p-type silicon with concentration of $1.7 \times 10^{18}$ $cm^{-3}$ at 300°K.

Figure 5-11

**PARAMETER:** Wavelength

**MATERIAL:** Silicon




**FORM** Bulk, polycrystalline

**THICKNESS** not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 4-12 μ

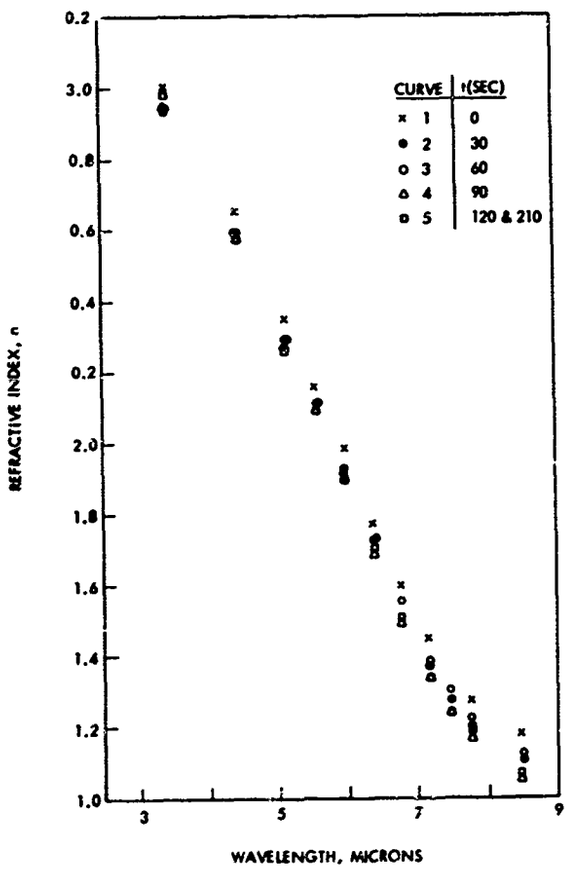
**TEMPERATURE** ~298 °K

**METHOD** Reflection

**REFERENCE** Simon (4799)

**REMARKS** Resistivity = 0.7 ohm-cm

Figure 5-12




**THICKNESS** not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 3.5-8.5 μ

**TEMPERATURE** ~298 °K

**METHOD** Reflection

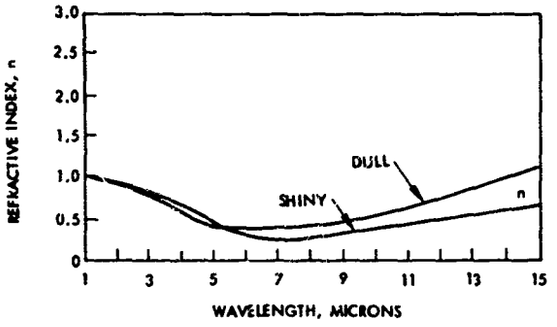
**REFERENCE** Spitzer, et al., (13860)

**REMARKS** Phosphorus-doped n-type silicon with concentration at 298°K of $7.5 \times 10^{19}$ cm$^{-3}$. Material vacuum-heat treated at 1310°K.

Figure 5-13

PARAMETER: Wavelength

MATERIAL: Silicon




FORM p-type surface on n-type substrate

THICKNESS $1 \times 10^{-2}$ (p-type) mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 1-15 μ

TEMPERATURE ~298 °K

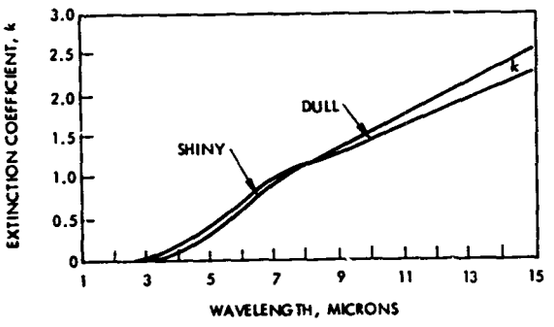
METHOD Reflection

REFERENCE Hall (13466)

REMARKS p-type surface produced by doping with boron.

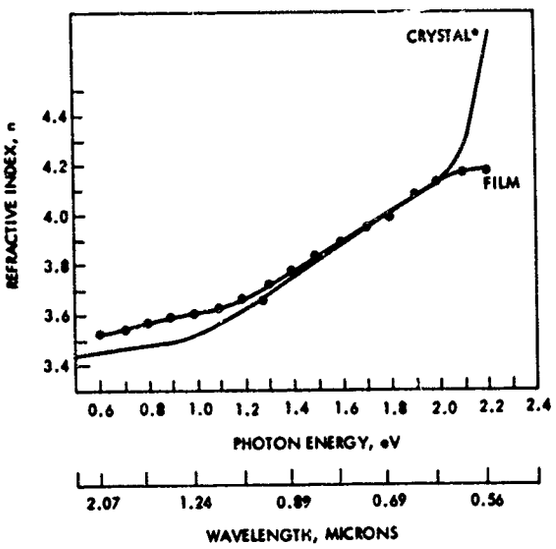
Figure 5-14

Figure 5-15



PARAMETER: Wavelength

MATERIAL: Silicon




* CRYSTAL DATA CALCULATED FROM REF (194)

Published with permission
Copyright © 1968 Elsevier
Publishing Company

FORM Film, amorphous

THICKNESS $(0.4\text{-}3.25) \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.55-2.2 μ

TEMPERATURE 298 °K

METHOD

REFERENCE Grigorovici & Vancu (35455)

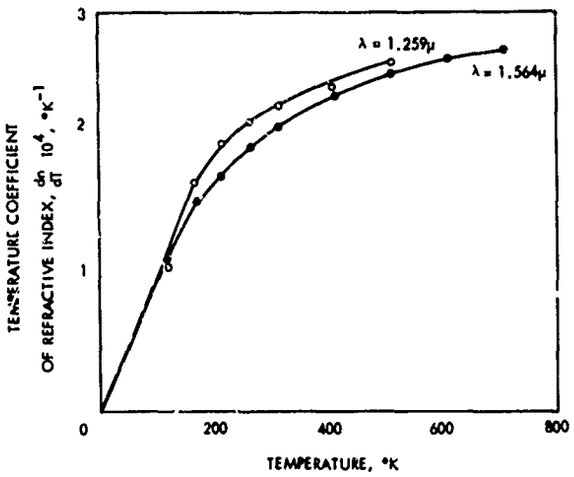
REMARKS Film produced by evaporation of pure silicon single crystal (resistivity = 10 ohm-cm) at $< 1 \times 10^{-5}$ torr using electron bombardment and lower end of silicon as crucible.

Note: crystal data refer to single crystals.

Figure 5-16

PARAMETER: Temperature

MATERIAL: Silicon




Published with permission
Copyright © 1959 Pergamon Press

FORM Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.26-1.56 μ

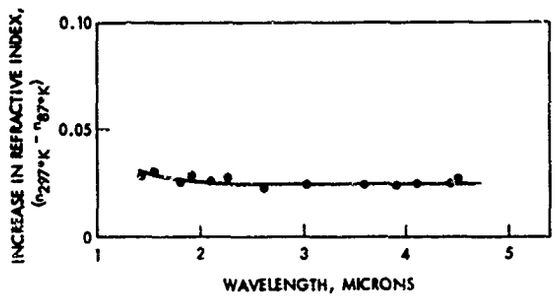
TEMPERATURE 109-750 °K

METHOD Deviation

REFERENCE Lukes (3382)

REMARKS p-type silicon, resistivity = 380 ohm-cm.

Figure 5-17




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0-4.5 μ

TEMPERATURE 87, 297 °K

METHOD Deviation

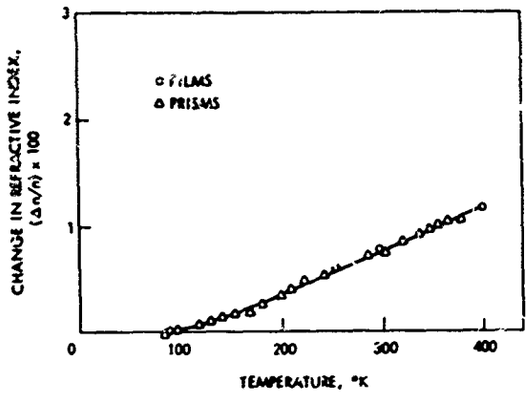
REFERENCE Cardona (2569)

REMARKS

Figure 5-18

PARAMETER: Temperature

MATERIAL: Silicon




FORM Single Crystal Film & Prism

THICKNESS Film 0.003-01010 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 3.0 μ

TEMPERATURE 77-400 °K

METHOD Interference for films, deviation for prism.

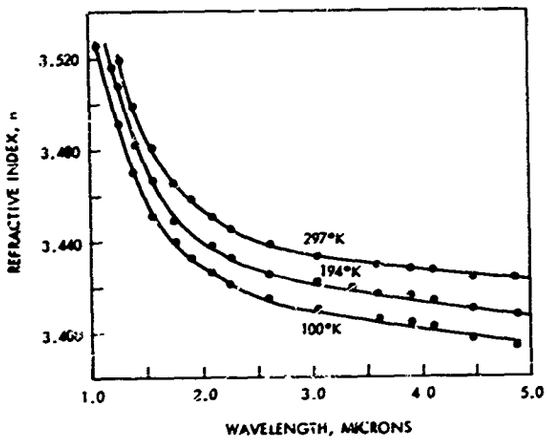
REFERENCE Cardona, et al. (620)

REMARKS

Equation:

$$(1/n)(dn/dT) = (3.9 \pm 0.4) \times 10^{-5} \ (^{\circ}K)^{-1}$$

Figure 5-19




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.1-4.8 μ

TEMPERATURE 100-297 °K

METHOD Deviation

REFERENCE Cardona, et al. (620)

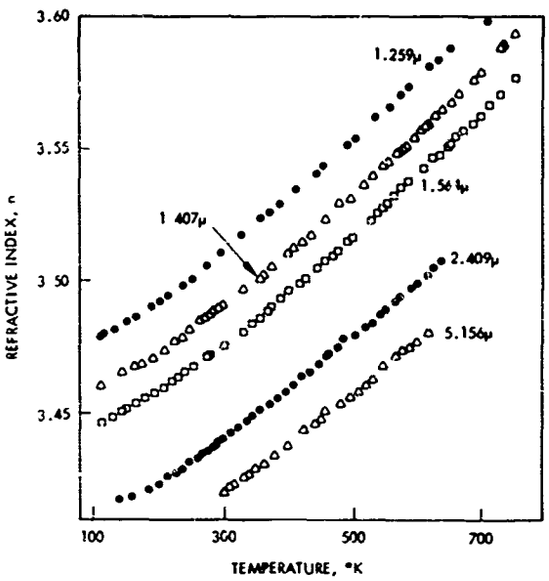
REMARKS

Figure 5-20

Published with permission
Copyright ©1959 Pergamon Press

PARAMETER: Temperature

MATERIAL: Silicon




Published with permission
Copyright © 1960 Czechoslovak
Academy of Sciences

FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.3-5.2 μ

TEMPERATURE 109-750 °K

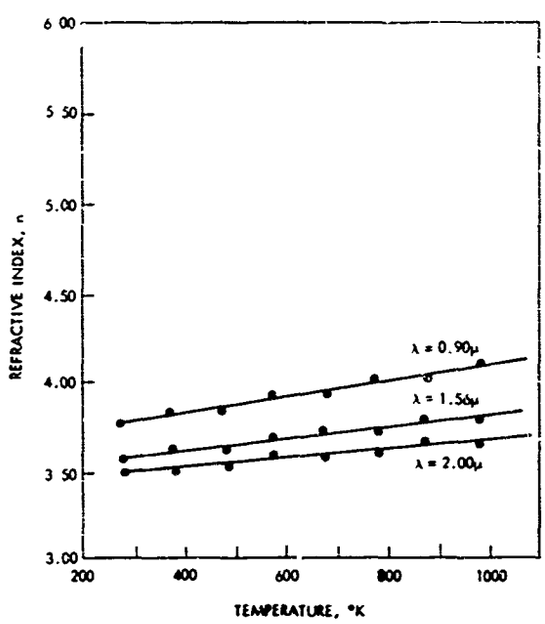
METHOD Deviation

REFERENCE Lukes (4541)

REMARKS p-type silicon,

Resistivity = 380 ohm-cm.

Figure 5-21




THICKNESS 1.77 (Bulk) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.9-2.0 μ

TEMPERATURE 280-960 °K

METHOD Emissivity

REFERENCE Sato (29333)

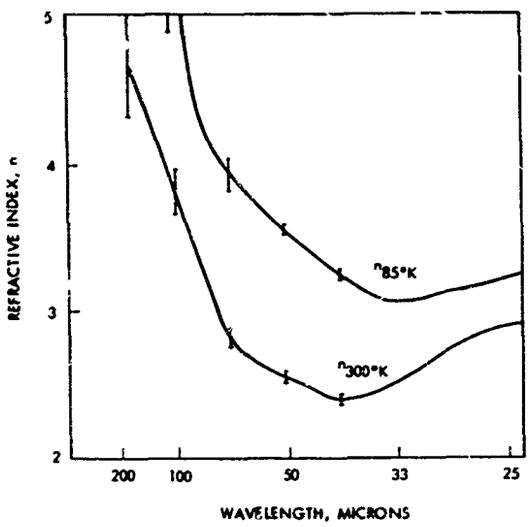
REMARKS n-type silicon, p-doped,

resistivity = 15 ohm-cm.

Figure 5-22

**PARAMETER:** Temperature

**MATERIAL:** Silicon




**FORM** Bulk

**THICKNESS** 0.010 mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 25-180 μ

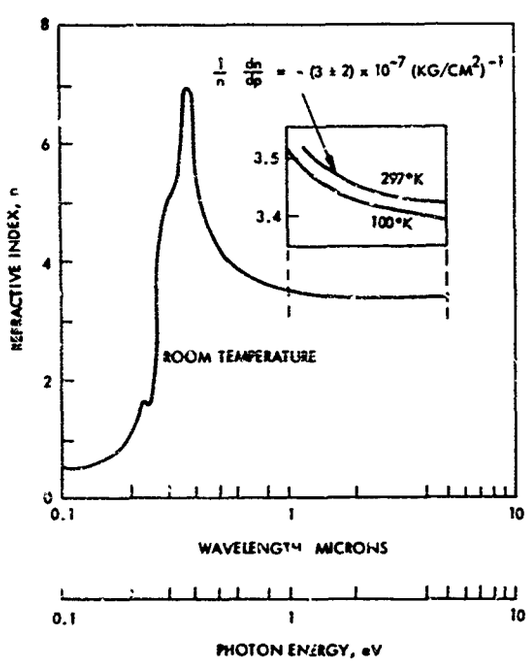
**TEMPERATURE** 85, 300 °K

**METHOD** Reflection

**REFERENCE** Balkanski and Besson (22653)

**REMARKS** Phosphorus-doped n-type silicon at concentration of $2.9 \times 10^{17}$ $cm^{-3}$ at 300°K.

Figure 5-23




**THICKNESS** not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.1-5 μ

**TEMPERATURE** 100, 297 °K

**METHOD** not stated

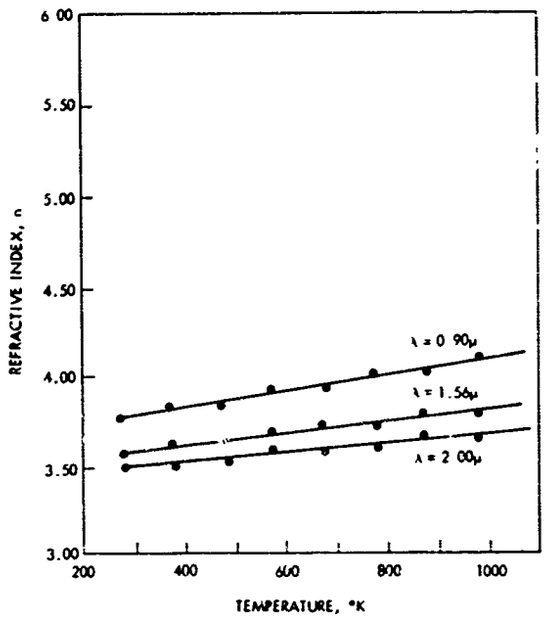
**REFERENCE** Evans (26567)

**REMARKS**

Figure 5-24

**PARAMETER:** Temperature

**MATERIAL:** Silicon




**FORM** Bulk

**THICKNESS** 1.77 mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.9 - 2.0 μ

**TEMPERATURE** 280 - 960 °K

**METHOD** Emissivity*

**REFERENCE** Sato (29333)

**REMARKS** n-type silicon, phosphorus-doped, resistivity = 15 Ω-cm.

Figure 5-25

*Calculated from:

$$\text{Emissivity} = \frac{4n}{(n+1)^2}$$

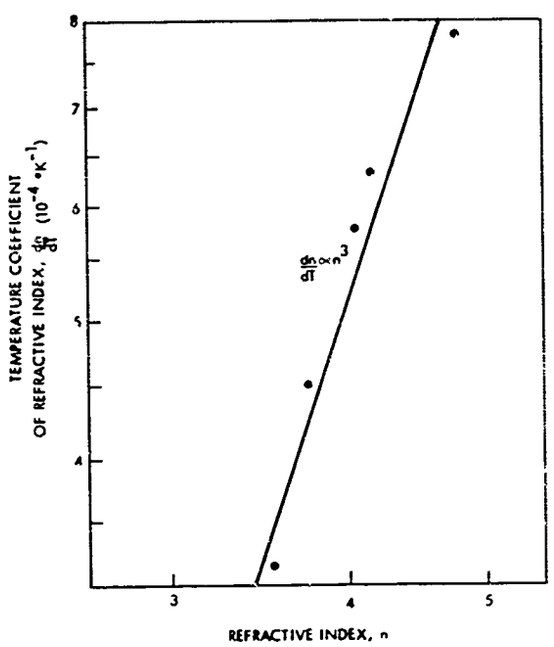
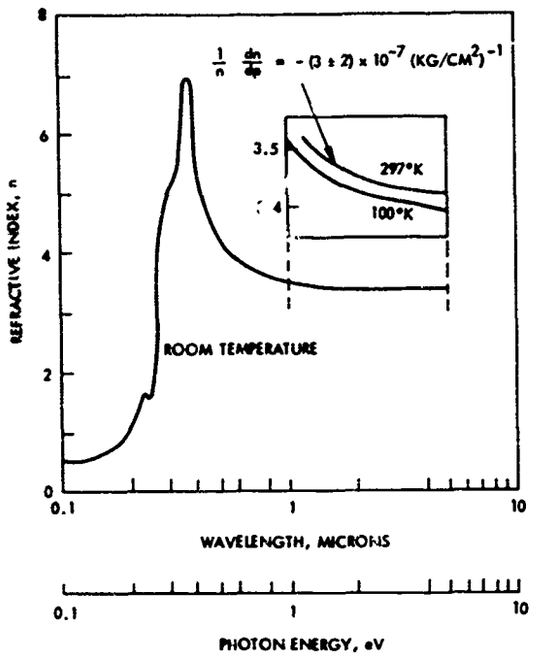



Figure 5-26

**PARAMETER:** Pressure

**MATERIAL:** Silicon




**FORM** Bulk

**THICKNESS** not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.1-5.0 μ

**TEMPERATURE** 297 °K

**METHOD** not stated

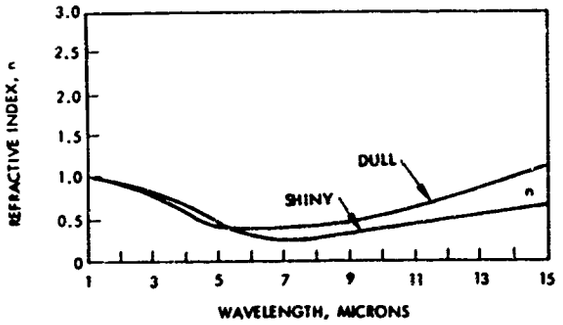
**REFERENCE** Evans (26567)

**REMARKS**

Figure 5-27

PARAMETER: Surface Condition

MATERIAL: Silicon




FORM p-type surface on n-type substrate

THICKNESS $1 \times 10^{-2}$ (p-type) film: mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 1-15 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Hall

REMARKS p-type surface produced by doping with boron.

Figure 5-28

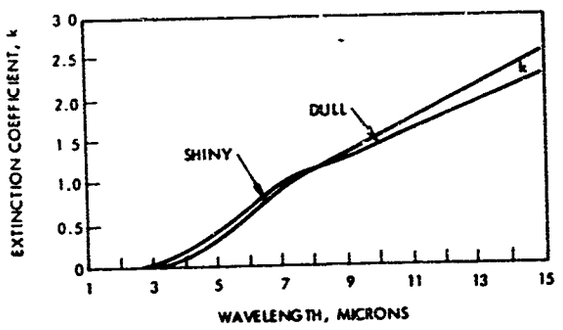



Figure 5-29

## GERMANIUM

### INTRODUCTION

Germanium is a semiconductor that has found application in infrared optics, transistors, diodes, rectifiers, thermoelectric devices and in brazing alloys. Recovery of germanium from ores involves a series of steps including pyro and hydrometallurgy to produce a germanium concentrate, chlorination to obtain a purer germanium tetrachloride, hydrolysis to produce still purer germanium dioxide and reduction of the oxide to the metal with zinc. This "first reduction metal" is zone refined to produce semiconductor grade germanium, and an increase in resistivity is accomplished from a minimum of 5 ohm-cm. for first reduction metal to a minimum of 40 ohm-cm. for the zone-refined metal. The resistivity of intrinsic germanium is 47 ohm-cm.

The physical properties of intrisic germanium are summarized in Table 1-1, and its optical transmission spectrum is plotted in Figure 1-3. Impurities in germanium have an effect on several properties including electrical resistivity and optical transmission. Indeed, even films prepared by evaporation of highly purified intrinsic germanium have shown to be p-type germanium with a resistivity of 3 to 10 ohm-cm, [Ref: Courvoisier, [1963]]. It is therefore apparent that a comparison of optical properties of evaporated films, measured by various workers, may be unrealistic because of different doping levels.

Doping levels are often expressed in terms of room temperature resistivity and Figure 5-30 permits the conversion between electrical resistivity and impurity concentration, at 300°K.

### DATA

All data presentations for germanium are listed in Table 5-5 and a summary of wavelength and temperature coverage is plotted in Figure 5-31.

Figure 5-32 presents a comparison in refractive indices of bulk and film germanium and also provides an introductory presentation of

PRECEDING PAGE BLANK

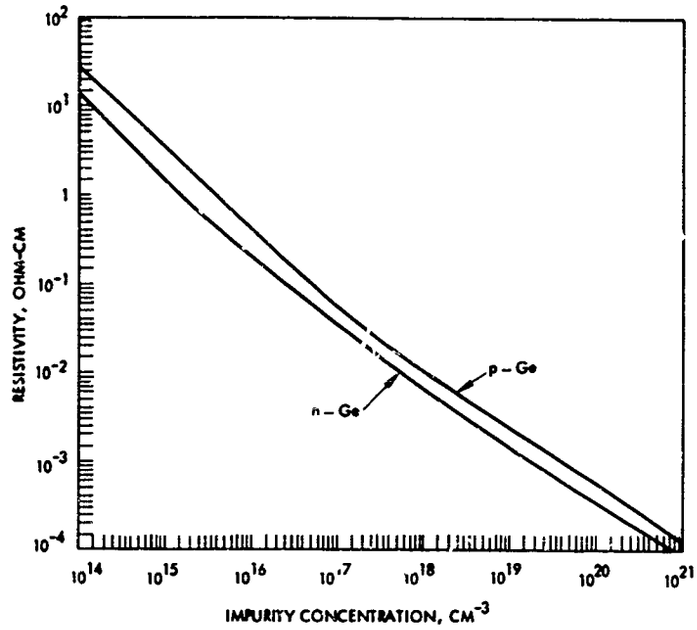



Figure 5-30. Resistivity versus Impurity Concentration for Ge, 300°K

Ref: Sze and Irvin (34530)

the effect of the nature of the evaporation atmosphere during film deposition. Data in Figure 5-32 as well as subsequent Figures show a consistently higher refractive index for films as compared to bulk germanium. Some observers [Ref: Wales, et al. (31497)] believe that this difference is caused by the presence of at least one additional loosely bonded electron than normal at the surface of the crystallites. Germanium films, deposited onto substrates that are below 673°K, are amorphous and will assume the refractive index of bulk material after annealing; annealing of such films caused crystallite formation. Similarly, deposition onto heated substrates (>673°K) resulted in the formation of films having bulk refractive index. Figures 5-33 to 5-48 and Tables 5-6 to 5-10 present additional spectral data for the refractive index of bulk and film germanium. As was the case with silicon, no generalization is possible for the effect of doping on the refractive

## Table 5-5. List of Germanium Data

| Figure | Table | n or k | Form | Crystal | Wavelength Range (microns) From | Wavelength Range (microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-32 | | n | Bulk, Film | * | 1.0 | 6.0 | Data comparison | Wavelength |
| 5-33 | | n | Bulk | Single | 0.6 | 1.7 | 300°K | Wavelength |
| 5-34 | | n | Bulk | Single | 0.6 | 1.7 | 120°K | Wavelength |
| 5-35 | | n | Bulk | Single | 2 | 16 | | Wavelength |
| 5-36 | | n | Bulk | * | 1.5 | 13 | | Wavelength |
| 5-37 | | n | Bulk | Single | 0.6 | 5.5 | 87-297°K | Wavelength |
| 5-38 | | n | Bulk | * | 0.8 | 5.5 | Several doping levels | Wavelength |
| 5-39 | | n | Bulk | Single | 0.1 | 1.8 | | Wavelength |
| | 5-6 | n | Bulk | Single | 25 | 143 | 7.5, 297°K | Wavelength |
| 5-40 | | n | Bulk | Single | 0.8 | 15 | | Wavelength |
| | 5-7 | n | Bulk | Single | 2.0 | 2.4 | | Wavelength |
| 5-41 | | n | Bulk | | 70 | 500 | | Wavelength |
| | 5-8 | n | Bulk | Single, polycryst | 2 | 16 | | Wavelength |
| | 5-9 | n | Bulk | | 1.8 | 2.6 | | Wavelength |
| 5-42 | | n | Bulk | * | 4 | 14 | | Wavelength |
| 5-43 | | n | Bulk | * | 5 | 35 | n-doped, p-doped | Wavelength |
| 5-44 | | k | Bulk | * | 12 | 35 | n-doped | Wavelength |
| | 5-10 | n | Film | * | 8.7 | 12.4 | 77, 300°K | Wavelength |
| 5-45 | | n | Film | | 1.0 | 5.0 | | Wavelength |
| 5-46 | | n | Film | * | 0.6 | 10 | | Wavelength |
| 5-47 | | n | Film | Polycryst | 0.7 | 3.1 | p-doped | Wavelength |
| 5-48 | | n | Film | * | 0.85 | 2.5 | | Wavelength |
| 5-49 | | n | Bulk | Single | 1.8 | 5.5 | n-doped | Temperature |
| 5-50 | | n | Bulk | * | 2.0 | 2.5 | n-doped | Temperature |
| 5-51 | | dn/dT | Bulk | | 2.0 | 2.5 | n doped | Temperature |
| 5-52 | | $n^2$ | Bulk | Single | 1.5 | 2.2 | 80-460°K | Temperature |
| | 5-11 | n | Bulk | * | 23 | 143 | 7.5, 297°K | Temperature |

*Not stated.

Table 5-5 (continued)

| Figure | Table | n or k | Form | Crystal | Wavelength Range (microns) From | To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-53 | | n | Bulk | Single | 0.6 | 1.7 | 300°K | Temperature |
| 5-54 | | n | Bulk | Single | 0.6 | 1.7 | 120°K | Temperature |
| 5-55 | | n | Bulk | * | 1.8 | 5.3 | 87-297°K | Temperature |
| 5-56 | | Δn/n | Bulk, Film | * | 3.0 | 3.0 | 90-400°K | Temperature |
| | 5-12 | dn/dT | * | * | 2.25 | 2.25 | | Temperature |
| | 5-13 | n | Bulk | Single | 2.0 | 2.4 | | Temperature |
| | 5-14 | n | Film | * | 8.7 | 12.4 | 77-300°K | Temperature |
| 5-57 | | Δn/n | Film | * | 2.0 | 4.0 | 77-395°K | Temperature |
| | 5-15 | (1/n)dn/dp | Film | * | 3.0 | 3.0 | | Pressure |
| | 5-16 | (1/n)dn/dp | Film | * | 3 | 3 | From RF dielectric data | Pressure |
| | 5-17 | (1/n)dn/dp | Film | * | 2.0 | 4.0 | | Pressure |
| | 5-18 | n | Film | * | 2.64 | 2.64 | 0.07-6.5μ Thickness | Film Thickness |
| 5-58 | | n | Film | * | 2.2 | 2.2 | Ge/ZnS Film | Film Composition |
| 5-59 | | n | Film | * | 1.0 | 5.0 | | Film Deposition Rate |
| 5-60 | | n | Film | * | 1.0 | 5.0 | Air atmosphere | Atmosphere Film Deposition |
| 5-61 | | n | Film | * | 0.5 | 5.0 | Vacuum atmosphere | Atmosphere Film Deposition |
| 5-62 | | n | Film | * | 1.0 | 5.0 | Oxygen atmosphere | Atmosphere Film Deposition |
| 5-63 | | n | Film | * | 1.0 | 5.0 | Nitrogen atmosphere | Atmosphere Film Deposition |
| 5-64 | | n | Film | * | 1.0 | 5.0 | Nitrogen atmosphere | Atmosphere Film Deposition |
| 5-65 | | n | Film | * | 1.0 | 5.0 | Hydrogen atmosphere | Atmosphere Film Deposition |
| 5-66 | | n | Film | * | 1.0 | 5.0 | 273°K | Deposition Substrate Temperature |
| 5-67 | | n | Film | * | 1.0 | 5.0 | 373-473°K | Deposition Substrate Temperature |
| 5-68 | | n | Film | * | 1.0 | 5.0 | 673°K | Deposition Substrate Temperature |
| 5-69 | | n | Film | | 1.0 | 5.0 | 773-873°K | Deposition Substrate Temperature |
| 5-70 | | n | Film | Amorphous and polycryst. | 1.25 | 6.5 | 293-573°K | Deposition Substrate Temperature |
| 5-71 | | Δn | Bulk | * | 1.6 | 2.2 | | Electric Field |

*Not stated.

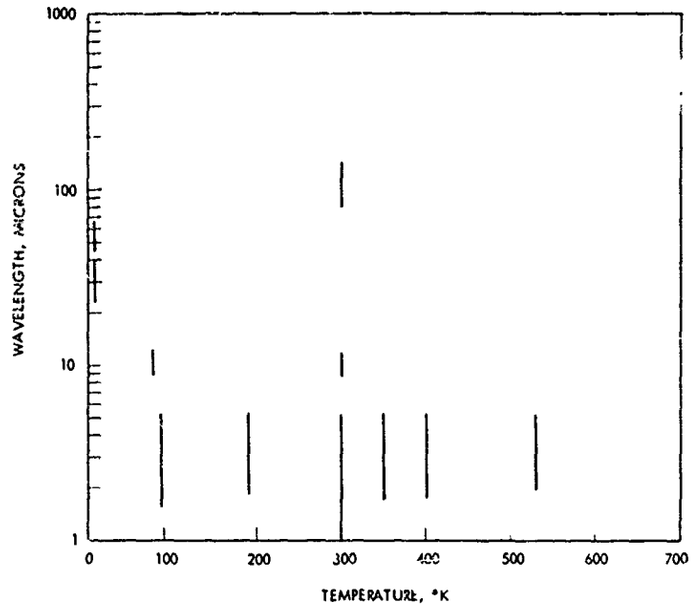



Figure 5-31. Wavelength and Temperature Range of Germanium Data

index. The effect of temperature on the refractive index is covered in Figures 5-49 to 5-57 and Tables 5-11 to 5-14. Tables 5-15 to 5-17 provide information on the effect of pressure on the refractive index. The effect of film thickness on the refractive index at 2.64 microns is indicated in Table 5-18 and a decreasing refractive index with increasing film thickness is observed. It is possible to make films with a continuously variable refractive index, as shown in Figure 5-58. These films are made by the simultaneous evaporation of germanium and zinc sulfide from two sources and may find application as absorption cut-off filters with variable cut-off frequency.

The refractive index of germanium is not greatly affected by the deposition rate, as shown in Figure 5-59. The effect of the nature of the deposition atmosphere is the subject of Figures 5-60 to 5-65 where the atmosphere consisted of air, vacuum, oxygen, nitrogen and hydrogen, respectively, with the gases at a pressure of approximately $1 \times 10^{-4}$ Torr. Except for a slight lowering in refractive index after

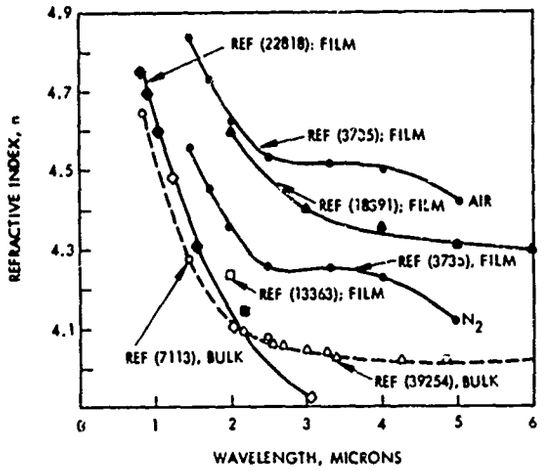
deposition in oxygen, no significant effect was observed. The low index from deposition in an oxygen environment may be caused by the formation of germanium dioxide, having a refractive index of approximately two in the near-infrared.

The substrate temperature during deposition has an effect on the crystallinity of the film. According to Davey [1961], germanium films which are deposited at a substrate temperature below 448°K, are amorphous. Data by Wales, et al. (31497) indicate a lower refractive index for films, deposited on hot substrates, (Figure 5-66 to 5-69). This is in contrast to the results of Gisin and Ivanov (41222), Figure 5-70, who obtained a higher refractive index for substrates at 523 - 573°K than at 403 - 423°K, their refractive indices for 403-423°K and 293 - 303°K were nearly identical, indicative of an amorphous state at both lower temperature ranges.

The dependence of the refractive index on the electric field is illustrated in Figure 5-71 in a study of the Franz-Keldysh Effect.

PARAMETER: Wavelength

MATERIAL. Germanium




FORM Bulk and Film

THICKNESS Various, not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 6 μ

TEMPERATURE ~298 °K

METHOD Various

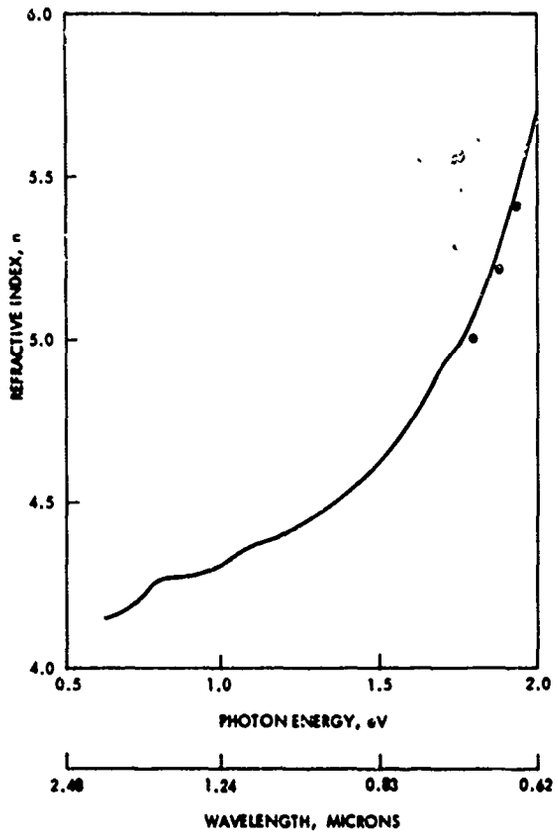
REFERENCE Wales, et al. (31497)

REMARKS

Figure 5-32

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.6 - 1.7 μ

TEMPERATURE 120, 300 °K

METHOD Reflection

REFERENCE Potter (27255)

REMARKS

Figure 5-33
(300°K)

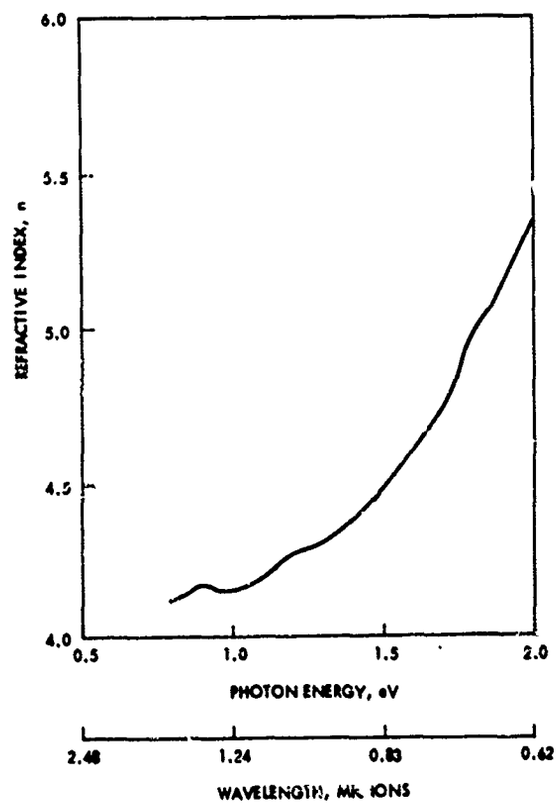
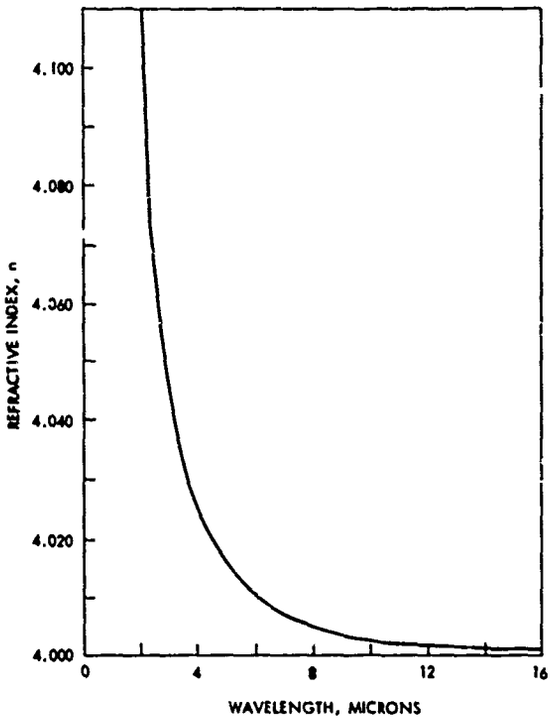



Figure 5-34
(120°K)

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 16 μ

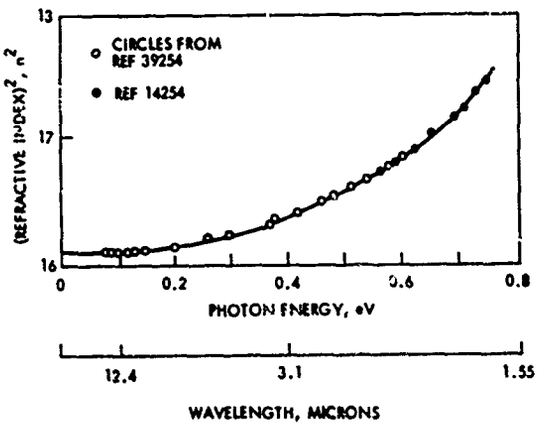
TEMPERATURE 300 °K

METHOD Deviation

REFERENCE Salzberg and Villa (3900)

REMARKS

Figure 3-35




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.5 - 13 μ

TEMPERATURE 291 °K

METHOD Deviation

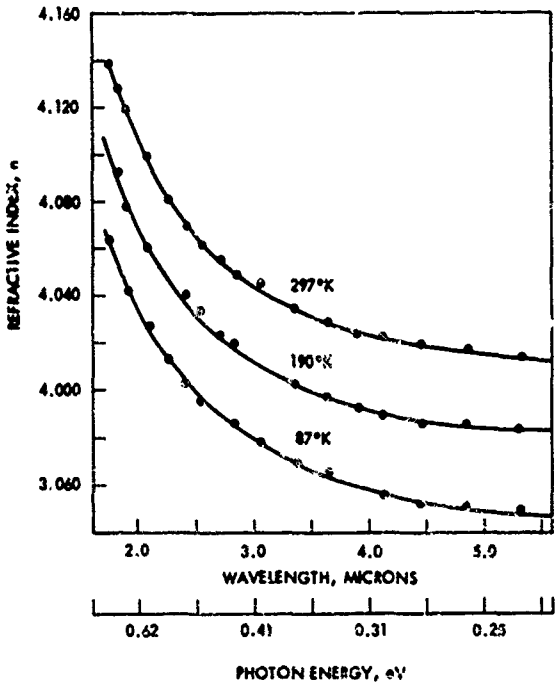
REFERENCE Kornfeld (14254)

REMARKS Resistivity = 50 ohm-cm

Figure 5-36

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk. Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.6 - 5.5 μ

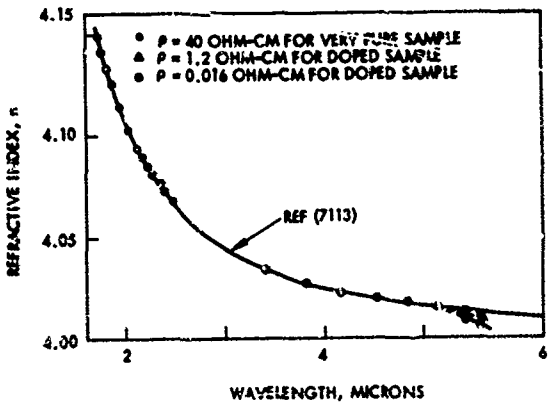
TEMPERATURE 87 - 297 °K

METHOD Deviation

REFERENCE Cardona, et al. (620)

REMARKS

Figure 5-37




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 5.5 μ

TEMPERATURE 300 °K

METHOD Deviation

REFERENCE Lukes (3915)

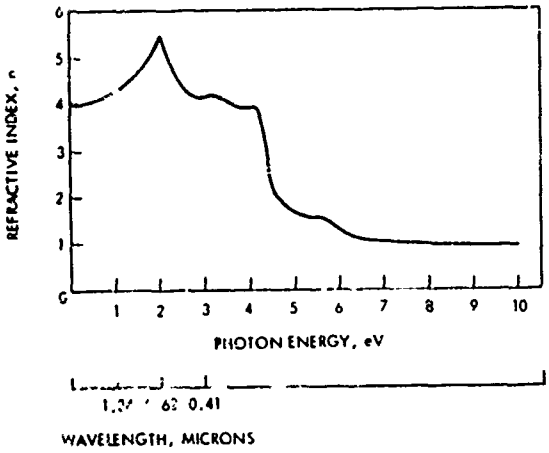
REMARKS Pure and n-type germanium, resistivity shown on graph.

Figure 5-38

Published with permission
Copyright © 1959 Pergamon Press

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.1 - 1.8 μ

TEMPERATURE 300 °K

METHOD Reflection

REFERENCE Philipp and Taft (7113)

REMARKS Data above 1.77 Microns taken from Salzberg and Villa (3900).

Figure 5-39

| Wavelength, (Microns) | Temperature °K | Refractive Index, n |
|---|---|---|
| 23-40 | 7.5 | 3.98 ±0.02 |
| 45-67 | 7.5 | 3.90 ±0.02 |
| 83-143 | 297 | 3.98 ±0.02 |

THICKNESS 0.5 - 2.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 23 - 143 μ

TEMPERATURE 7.5, 297 °K

METHOD Interference

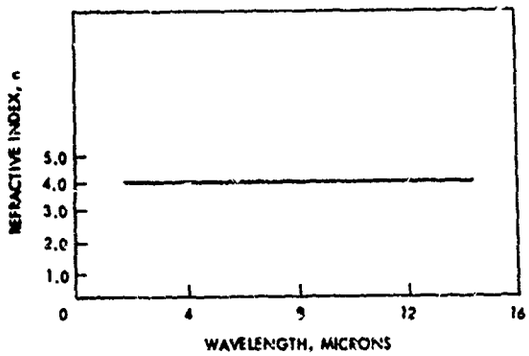
REFERENCE Aronson, et al. (16091)

REMARKS Crystal cut perpendicular to the [111] axis.

Table 5-6

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS ~7 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 15.2 μ

TEMPERATURE ~297 °K

METHOD Transmission, Reflection

REFERENCE Oswald and Schade (2139)

REMARKS Resistivity = 56 ohm-cm.

Figure 5-40

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 2.00 | 4.1254 |
| 2.10 | 4.1145 |
| 2.30 | 4.0980 |
| 2.40 | 4.0918 |

THICKNESS 3.06 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0 - 2.4 μ

TEMPERATURE 297.5 °K

METHOD Interference

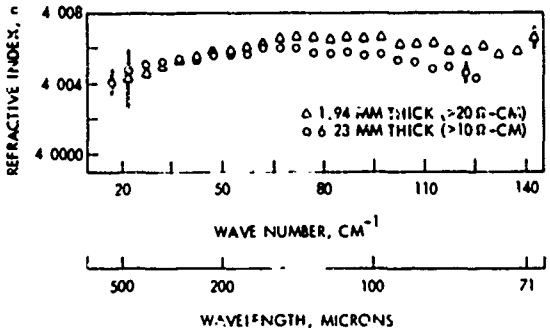
REFERENCE Rank, et al. (39713)

REMARKS Measurements in vacuo.

Table 5-7

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk

THICKNESS 1.89, 6.23 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 70 - 500 μ

TEMPERATURE ~300 °K

METHOD Interference

REFERENCE Randall and Rawcliffe (33251)

REMARKS Resistivity:

1.94 mm. sample, 20 ohm-cm.

6.23 mm. sample, 10 ohm-cm.

Figure 5-41

PARAMETER: Wavelength

MATERIAL: Germanium

| Wavelength (Microns) | Index: Single-crystal $n_1$* | Index: Single-crystal n | Index: Polycrystal n |
|---|---|---|---|
| 2.0581 | 4.1016 | 4.1016 | 4.1018 |
| 2.1526 | 4.0917 | 4.0919 | 4.0919 |
| 2.3126 | 4.0788 | 4.0786 | 4.0785 |
| 2.4374 | 4.0706 | 4.0708 | 4.0709 |
| 2.577 | 4.0610 | 4.0609 | 4.0608 |
| 2.7144 | 4.0554 | 4.0552 | 4.0554 |
| 2.998 | 4.0453 | 4.0452 | 4.0452 |
| 3.3033 | 4.0370 | 4.0369 | 4.0372 |
| 3.4188 | 4.0336 | 4.0334 | 4.0339 |
| 4.258 | 4.0217 | 4.0216 | 4.0217 |
| 5.866 | 4.0170 | 4.0170 | 4.0167 |
| 6.2.6 | 4.0092 | 4.0094 | 4.0095 |
| 8.66 | 4.0036 | 4.0043 | 4.0043 |
| 9.72 | 4.0026 | 4.0034 | 4.0033 |
| 11.94 | 4.0020 | 4.0026 | 4.0025 |
| 12.20 | 4.0018 | 4.0023 | 4.0020 |
| 13.02 | 4.0016 | 4.0021 | 4.0018 |
| 14.21 | 4.0015 | | |
| 15.08 | 4.0014 | | |
| 16.00 | 4.0012 | | |

*$n_1$ previously published data from Salzberg and Villa (3900)

FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 16 μ

TEMPERATURE 300 °K

METHOD Deviation

REFERENCE Salzberg and Villa (39254)

REMARKS Single and polycrystalline material

Table 5-8

| Wavelength (Microns) | Refractive Index, n |
|---|---|
| 1.80 | 4.143 |
| 1.85 | 4.135 |
| 1.90 | 4.129 |
| 2.00 | 4.116 |
| 2.10 | 4.104 |
| 2.20 | 4.092 |
| 2.30 | 4.085 |
| 2.40 | 4.078 |
| 2.50 | 4.072 |
| 2.60 | 4.068 |

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.8 - 2.6 μ

TEMPERATURE ~298 °K

METHOD Deviation

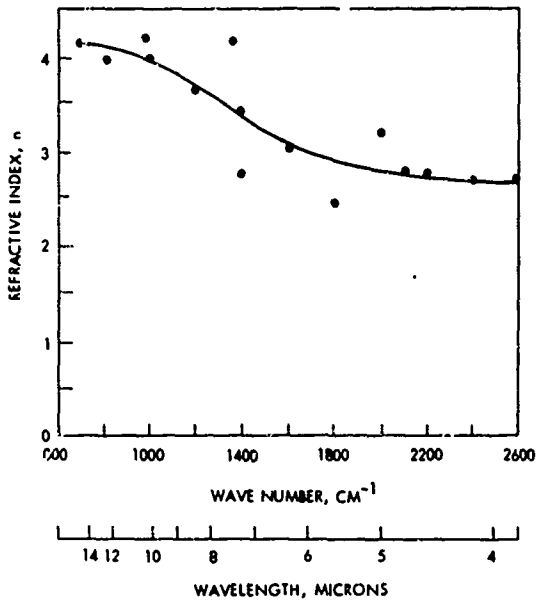
REFERENCE Briggs (13314)

REMARKS

Table 5-9

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk

THICKNESS ~0.8 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 4 - 14 μ

TEMPERATURE Not stated °K

METHOD Reflection

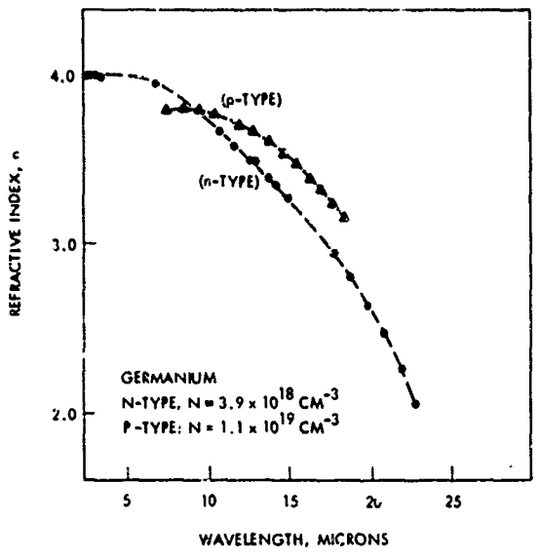
REFERENCE Simon (4799)

REMARKS n-type material with resistivity 1 ohm-cm at 297° K

Figure 5-42

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Bulk

THICKNESS $\sim 10^{-2}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 5 - 35 μ

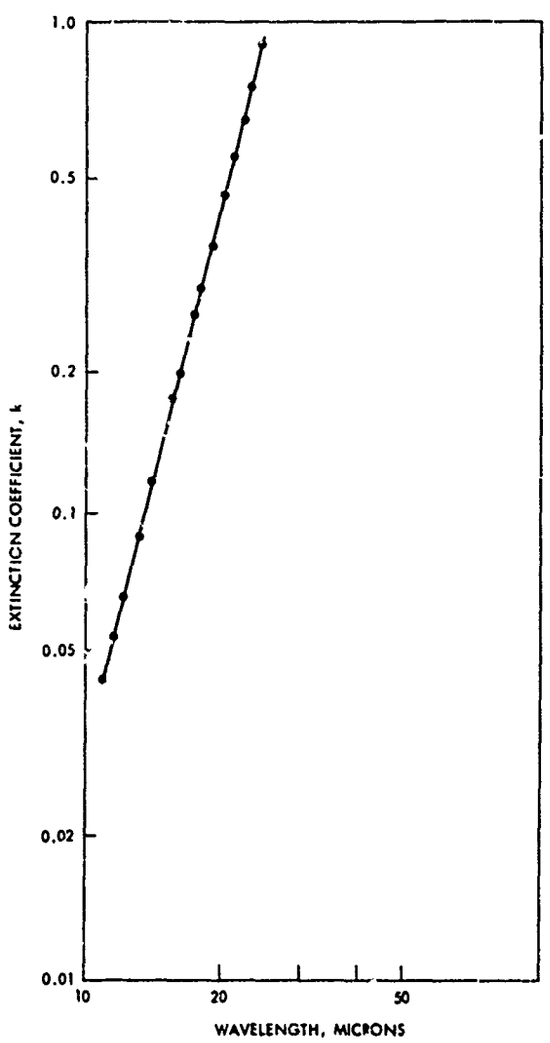
TEMPERATURE 297 °K

METHOD Transmission, Reflection

REFERENCE Spitzer and Fan (791)

REMARKS n-type, arsenic-doped material, concentration = $3.9 \times 10^{18}$ $cm^{3}$. p-type, gallium-doped, concentration = $1.1 \times 10^{19}$ $cm^{-3}$.

Figure 5-43




THICKNESS $\sim 10^{-2}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 12 - 35 μ

TEMPERATURE 297 °K

METHOD Transmission, Reflection

REFERENCE Spitzer and Fan (791)

REMARKS n-type, arsenic doped material, concentration = $3.9 \times 10^{18}$ $cm^{-3}$

Figure 5-44

PARAMETER: Wavelength

MATERIAL: Germanium

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | 77°K | 300°K |
| 8.66 | 3.77 | 3.92 |
| 9.4 | 3.81 | 3.90 |
| 10.2 | 3.81 | 3.93 |
| 11.22 | 3.81 | 3.92 |
| 12.35 | 3.82 | 3.93 |

FORM Film

THICKNESS 0.227 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 8.66 - 12.35 μ

TEMPERATURE 77, 300 °K

METHOD Interference

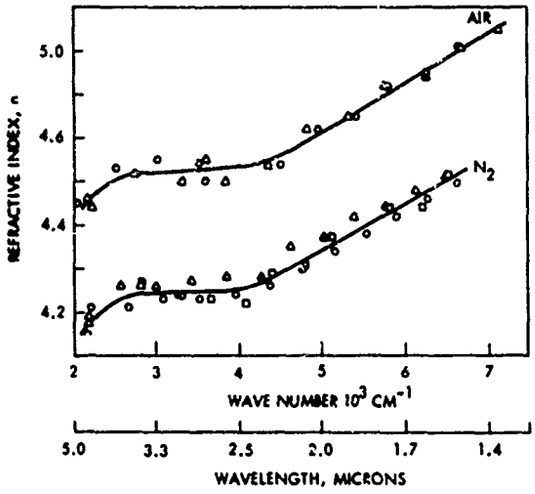
REFERENCE Collins (40273)

REMARKS

Table 5-10

PARAMETER: Wavelength

MATERIAL: Germanium




Air plots: O, layer with d = 1.092 μ; Δ, d = 1.010 μ.

Nitrogen plots: O, layer with d = 1.340 μ; Δ, d = 1.364 μ. □d = 1.449 μ. x determined from Brewster angle; remaining plots from geometric thickness of film.

FORM Film

THICKNESS (see remarks), ~$10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 5 μ

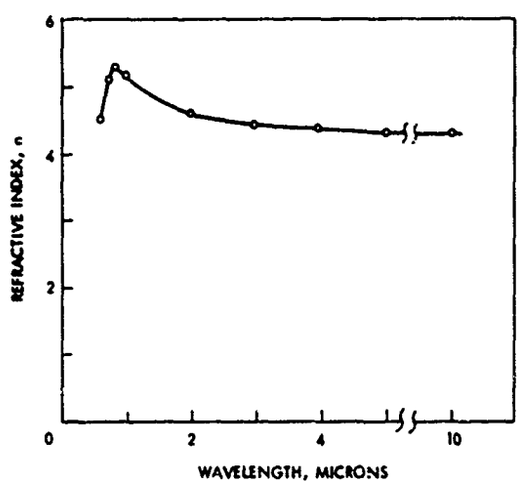
TEMPERATURE ~297 °K

METHOD Interference, Reflection

REFERENCE Huldt and Staflin (3735)

REMARKS Glass substrate;

Figure 5-45




THICKNESS $4 \times 10^{-5}$ - $1 \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.6 - 10 μ

TEMPERATURE 297 °K

METHOD Interference

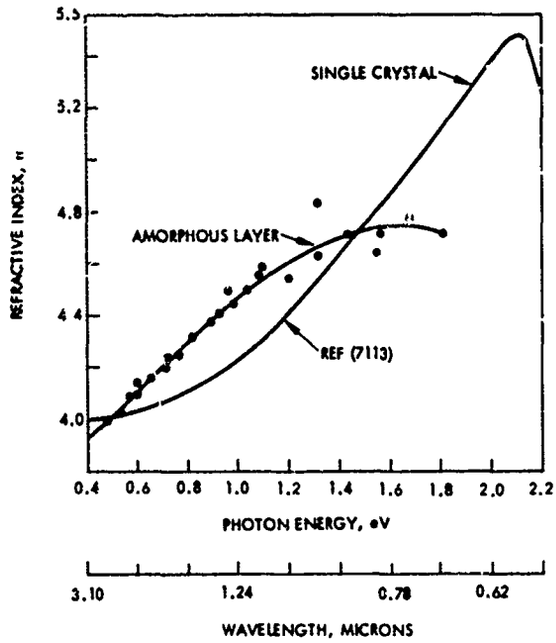
REFERENCE Brattain and Briggs (18391)

REMARKS

Figure 5-46

PARAMETER: Wavelength

MATERIAL: Germanium




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.7 - 3.1 μ

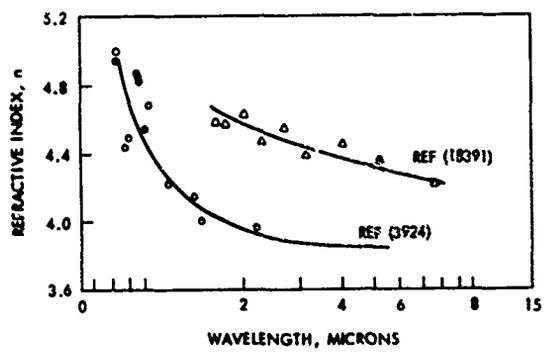
TEMPERATURE 297 °K

METHOD Transmission, Reflection

REFERENCE Tauc, et al. (22818)

REMARKS Amorphous polycrystalline layer is highly doped ($10^{18}$ - $10^{19}$ $cm^{-3}$), and was prepared by evaporation onto a cool (300° K) quartz substrate. Crystallites are ~$10^3$ Å in size.

Figure 5-47




THICKNESS $1 \times 10^{-5}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.85 - 2.5 μ

TEMPERATURE ~297 °K

METHOD Transmission, Reflection

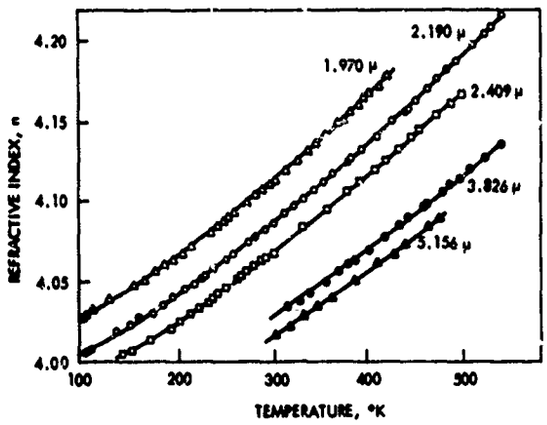
REFERENCE Lukes (3924)

REMARKS Film evaporated onto glass substrate.

Figure 5-48

PARAMETER: Temperature

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.8 - 5.5 μ

TEMPERATURE 100 - 530 °K

METHOD Deviation

REFERENCE Lukes (3915)

REMARKS n-type material with resistivity = 1.2 ohm-cm. at 300° K

Figure 5-49

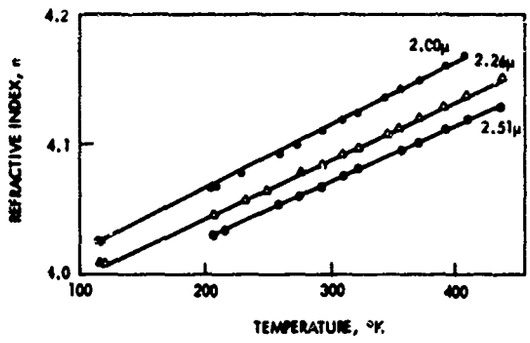
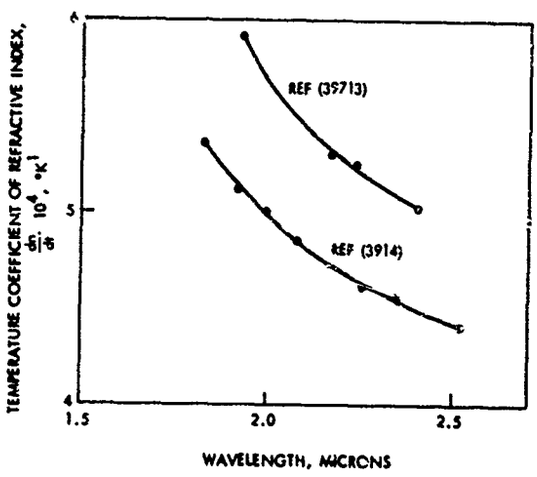



Figure 5-50




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0 - 2.5 μ

TEMPERATURE 116 - 440 °K

METHOD Deviation

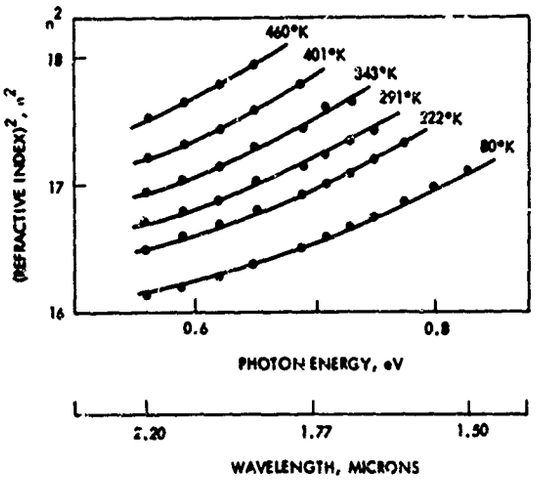
REFERENCE Lukes (3914)

REMARKS n-type germanium

Figure 5-51

PARAMETER: Temperature

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.5 - 2.2 μ

TEMPERATURE 80 - 460 °K

METHOD Deviation

REFERENCE Kornfeld (14254)

REMARKS Resistivity = 50 ohm-cm.

Figure 5-52

| Wavelength, (Microns) | Temperature °K | Refractive Index, n |
|---|---|---|
| 23-40 | 7.5 | 3.98 ±0.02 |
| 45-67 | 7.5 | 3.90 ±0.02 |
| 83-143 | 297 | 3.98 ±0.02 |

THICKNESS 0.5 - 2.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 23 - 143 μ

TEMPERATURE 7.5, 297 °K

METHOD Interference

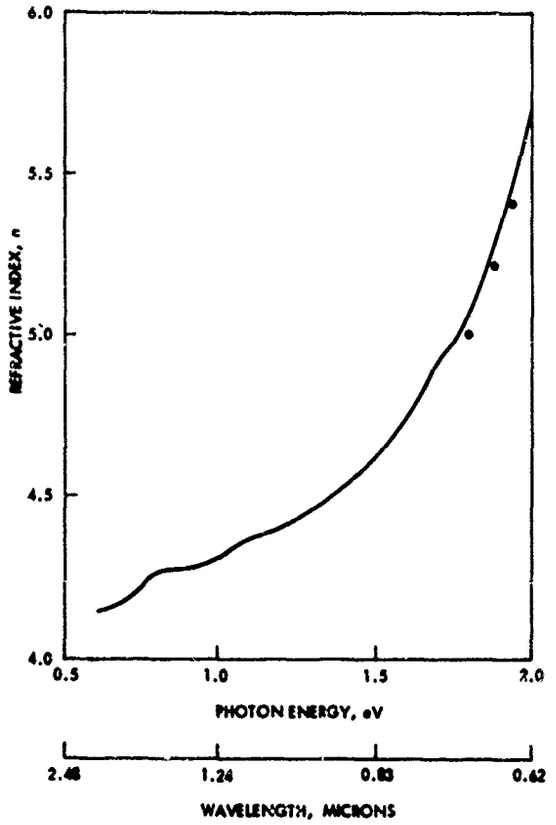
REFERENCE Aronson, et al. (16091)

REMARKS Crystal cut perpendicular to the [111] axis.

Table 5-11

PARAMETER: Temperature

MATERIAL: Germanium




FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.6 - 1.7 μ

TEMPERATURE 120, 300 °K

METHOD Reflection

REFERENCE Potter (27255)

REMARKS

Figure 5-53

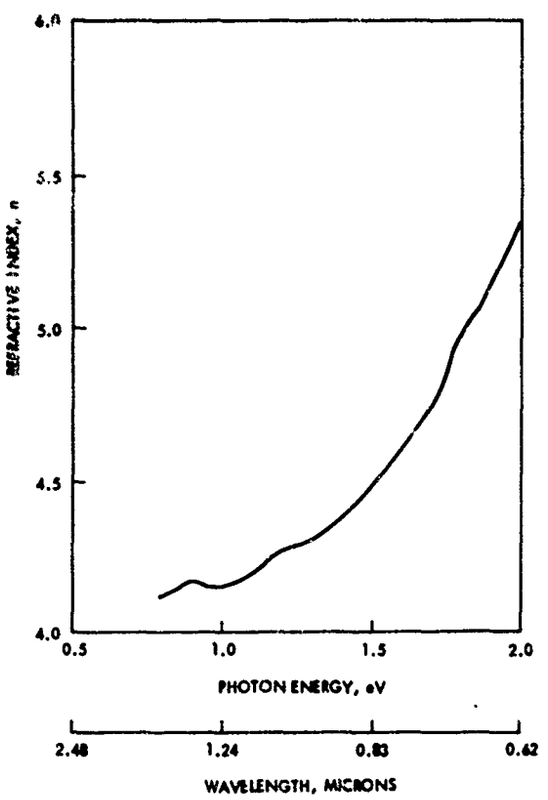
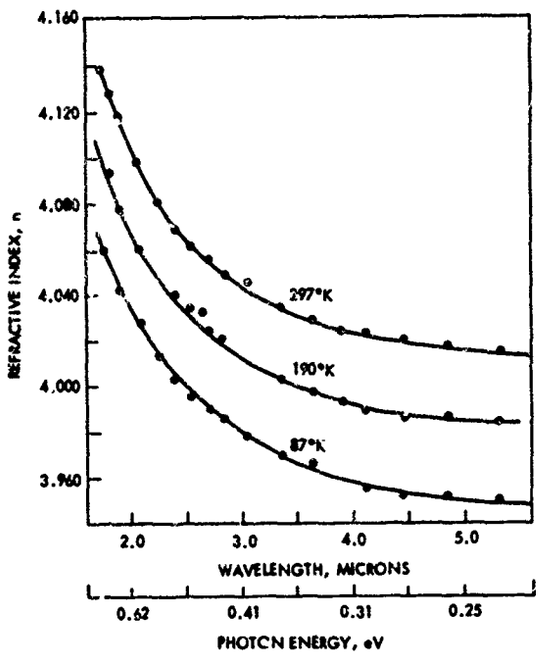



Figure 5-54

PARAMETER: Temperature

MATERIAL: Germanium




FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.8 - 5.3 μ

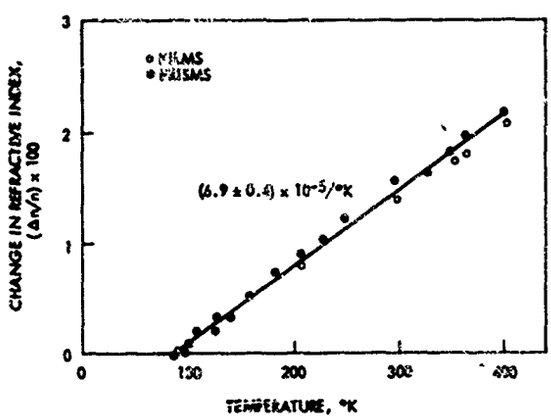
TEMPERATURE 87 - 297 °K

METHOD Deviation

REFERENCE Cardona (2569)

REMARKS

Figure 5-55




THICKNESS NA (Prism); Film mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 3.0 μ

TEMPERATURE 90 - 400 °K

METHOD Deviation, Interference

REFERENCE Cardona, et al. (620)

REMARKS

Figure 5-56

Published with permission
Copyright © 1959 Pergamon Press

PARAMETER: Temperature

MATERIAL: Germanium

$$dn/dT = 5.25 \times 10^{-4} (K°)^{-1}$$

FORM Not stated

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.25 μ

TEMPERATURE Not stated °K

METHOD Not stated

REFERENCE Rochow (8766)

REMARKS

Table 5-12

| Wavelength, (Microns) | Thermal Coefficient dn/dT, $(°K)^{-1}$ |
|---|---|
| 1.934 | $5.919 \times 10^{-4}$ |
| 2.174 | 5.285 |
| 2.246 | 5.251 |
| 2.401 | 5.037 |

THICKNESS 3.0574 (single crystal) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0 - 2.4 μ

TEMPERATURE 297.5 °K

METHOD Interference

REFERENCE Rank, et al. (39713)

REMARKS Measurements in vacuo. Thermal expansion contributed only 4% to dn/dT.

Table 5-13

PARAMETER: Temperature

MATERIAL: Germanium

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | 77°K | 300°K |
| 8.66 | 3.77 | 3.92 |
| 9.4 | 3.81 | 3.90 |
| 10.2 | 3.81 | 3.93 |
| 11.22 | 3.81 | 3.92 |
| 12.35 | 3.82 | 3.93 |

FORM Film

THICKNESS 0.227 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 8.66 - 12.35 μ

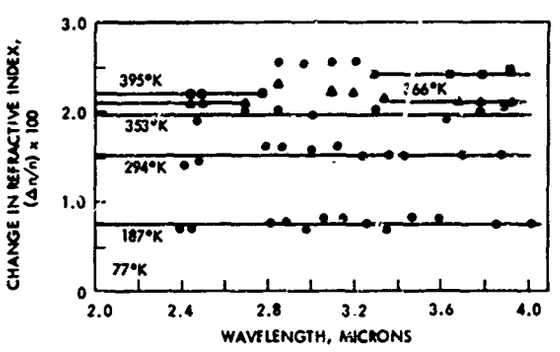
TEMPERATURE 77, 300 °K

METHOD Interference

REFERENCE Collins (40273)

REMARKS

Table 5-14




THICKNESS $1.2 \times 10^{-2}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0 - 4.0 μ

TEMPERATURE 77 - 395 °K

METHOD Interference

REFERENCE Cardona (2569)

REMARKS

Figure 5-57

PARAMETER: Pressure

MATERIAL: Germanium

$$(1/n)(dn/dP)_T = (-0.7 \pm 0.2) \times 10^{-6}\ cm^2 kg^{-1}$$

FORM Film mm

THICKNESS $(3\text{-}10) \times 10^{-3}$

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 3.0 μ

TEMPERATURE 297 °K

METHOD Interference

REFERENCE Cardona, et al. (620)

REMARKS Pressure range $0 - 1.42 \times 10^5$ psi

Table 5-15

$$(1/n)(dn/dP)_T = (-0.6 \pm 0.15) \times 10^{-6}\ cm^2 kg^{-1}$$

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH ~3 μ

TEMPERATURE 297 °K

METHOD RF dielectric

REFERENCE Cardona, et al. (620)

REMARKS Pressure range $0 - 1.42 \times 10^5$ psi

Table 5-16

PARAMETER: Pressure

MATERIAL: Germanium

FORM Film mm

THICKNESS $3.8 \times 10^{-3}$

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0 - 4.0 μ

TEMPERATURE 297 °K

METHOD Interference

REFERENCE Cardona (2569)

REMARKS Pressure range

$0 - 1 \times 10^5$ psi

$$(1/n)(dn/dP)_T = (-0.6 \pm 0.3) \times 10^{-6}\ cm^2 kg^{-1}$$

Table 5-17

PARAMETER: Film Thickness

MATERIAL: Germanium

| Film Thickness, (Microns) | Refractive Index, n |
|---|---|
| 0.07 | 3.43 |
| 0.09 | 4.12 |
| 0.1 | 4.07 |
| 0.18 | 4.24 |
| 0.26 | 4.23 |
| 0.375 | 3.75 |
| 1.52 | 4.0 |
| 2.57 | 3.98 |
| 6.5 | 3.62 |

FORM Film

THICKNESS As shown mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.64 μ

TEMPERATURE 300 °K

METHOD Interference

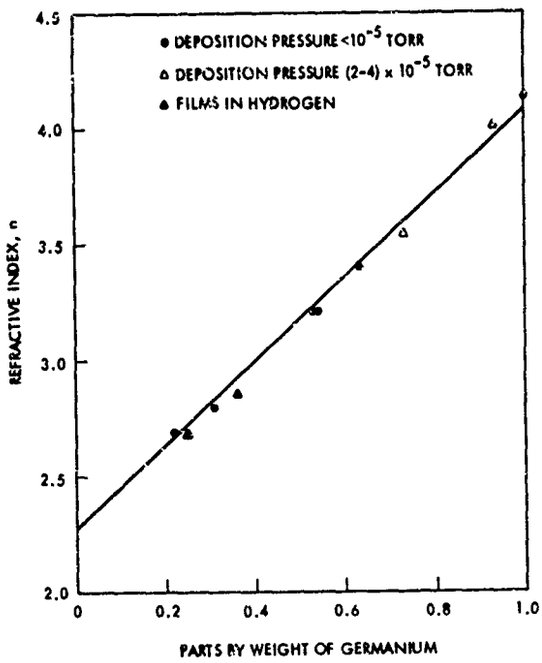
REFERENCE Wales, et al. (31497)

REMARKS Unheated substrate with electron beam heating.

Table 5-18

PARAMETER: Film Composition

MATERIAL: Germanium/ Zinc Sulfide




FORM Film, mixed (Ge + ZnS)

THICKNESS $(1.9 - 7.3) \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.2 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Jacobsson (40180)

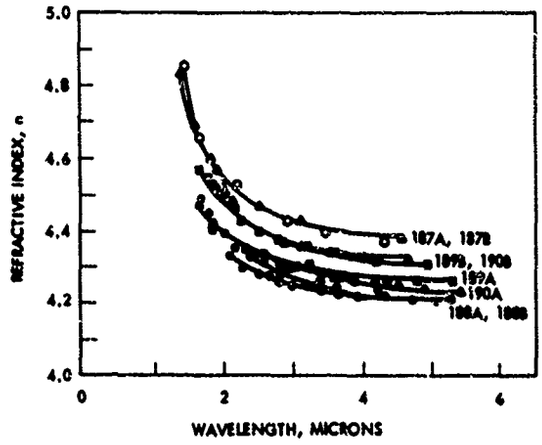
REMARKS Film produced by simultaneous evaporation from two sources.

NOTE: The absorption edge is displaced with a change in concentration, facilitating use of the film as variable cut-off filters.

Figure 5-58

PARAMETER: Film Deposition Rate

MATERIAL: Germanium




FORM Film

THICKNESS $(0.5 - 5) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 5.0 μ

TEMPERATURE ~300 °K

METHOD Transmission

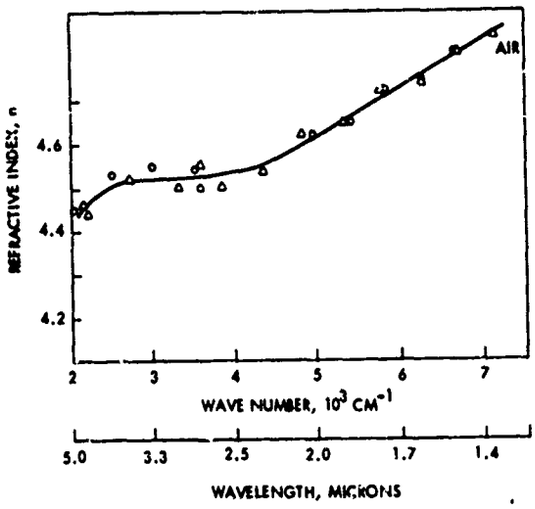
REFERENCE Wales, et al. (31497)

REMARKS Preparation on unheated substrate. Samples labelled "A" are at a higher deposition rate than "B". Source temperature is a function of number shown. "A" samples are at a higher deposition rate than "B" samples.

Figure 5-59

**PARAMETER:** Film Deposition Atmosphere

**MATERIAL:** Germanium




**FORM** Film

**THICKNESS** $10^{-3}$ mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.0 - 5.0 μ

**TEMPERATURE** ~297 °K

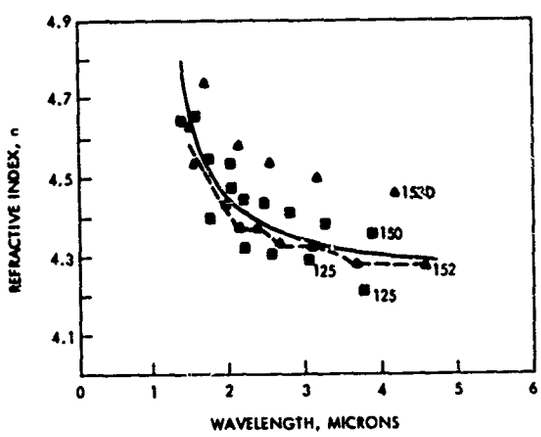
**METHOD** Interference, Reflection

**REFERENCE** Huldt and Staflin (3735)

**REMARKS** Glass substrate.

Layer thickness: O1.092 μ, Δ 1.010 μ.

Figure 5-60




**THICKNESS** $(0.5 - 5) \times 10^{-3}$ mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1 - 5.0 μ

**TEMPERATURE** ~300 °K

**METHOD** Transmission

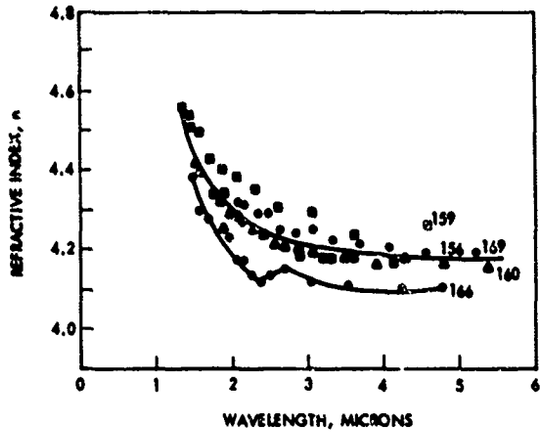
**REFERENCE** Wales, et al. (31497)

**REMARKS** Unheated substrate, electron beam heating, pressure = $1 \times 10^{-6}$ Torr.

Figure 5-61

PARAMETER: Film Deposition Atmosphere

MATERIAL: Germanium




FORM Film

THICKNESS $(0.5 - 5) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 5.0 μ

TEMPERATURE ~300 °K

METHOD Transmission

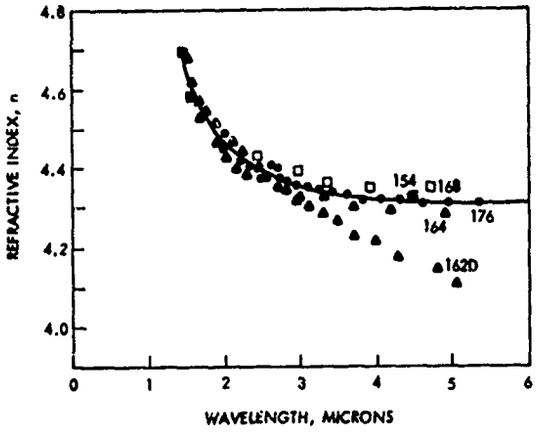
REFERENCE Wales, et al. (31497)

REMARKS Unheated substrate, electron beam heating, $1 \times 10^{-4}$ Torr oxygen pressure

Figure 5-62

PARAMETER: Film Deposition Atmosphere

MATERIAL: Germanium




FORM Film

THICKNESS $(0.5 - 5) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 5.0 μ

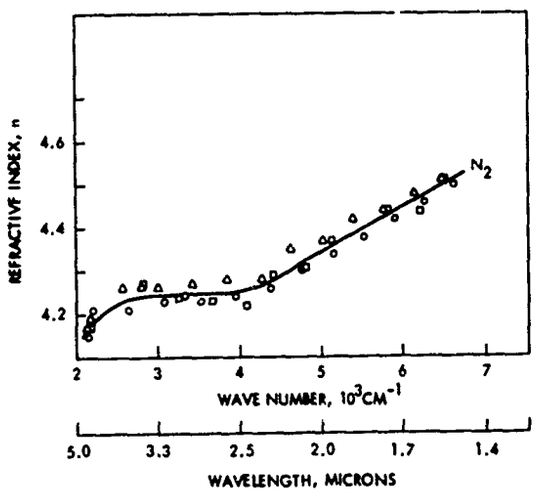
TEMPERATURE ~300 °K

METHOD Transmission

REFERENCE Wales, et al. (31497)

REMARKS Unheated substrate, electron beam heating, $1 \times 10^{-4}$ Torr nitrogen pressure.

Figure 5-63




THICKNESS $10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 5.0 μ

TEMPERATURE 297 °K

METHOD Interference, Reflection

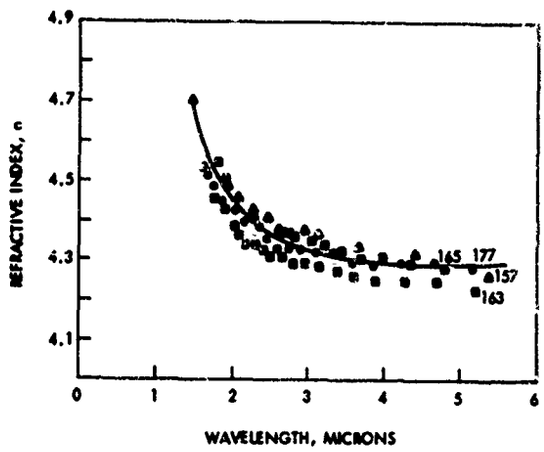
REFERENCE Huldt and Staflin (3735)

REMARKS Glass substrate. Layer thickness: O 1.340 μ; △1.364 μ; □1.449 μ.

Figure 5-64

PARAMETER: Film Deposition Atmosphere

MATERIAL: Germanium




FORM Film

THICKNESS $(0.5 - 5) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 5.0 μ

TEMPERATURE ~300 °K

METHOD Transmission

REFERENCE Wales, et al. (31497)

REMARKS Unheated substrate, electron beam heating, $1 \times 10^{-4}$ Torr hydrogen pressure.

Figure 5-65

Film Deposition

**PARAMETER:** Substrate Temperature

**MATERIAL:** Germanium

**FORM** Film

**THICKNESS** $(0.5 - 5) \times 10^{-3}$ mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1 - 5 μ

**TEMPERATURE** 300 °K

**METHOD** Transmission

**REFERENCE** Wales, et al. (31497)

**REMARKS** Substrate heated from carbon boat. Pressure = $1 \times 10^{-6}$ Torr.

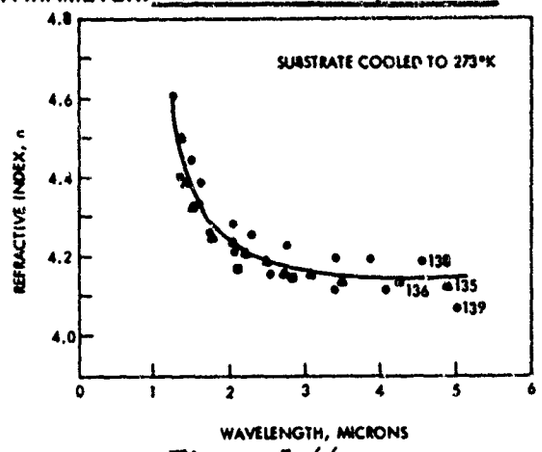



Figure 5-66

(273° K)

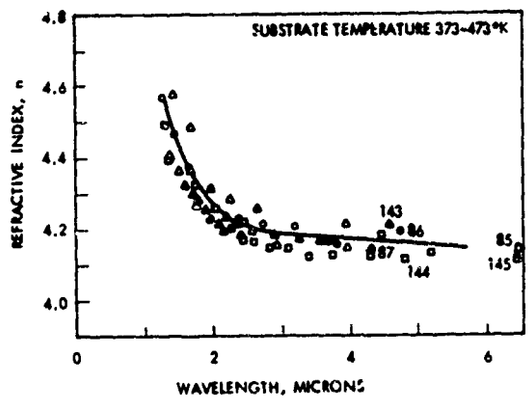



Figure 5-67

(373 - 473° K)

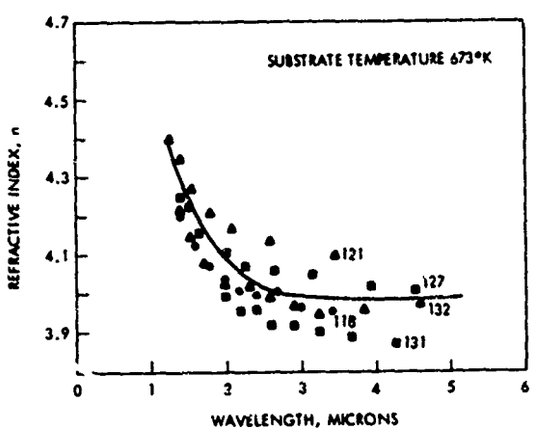



Figure 5-68

(673° K)

Figure 5-66 to 5-69

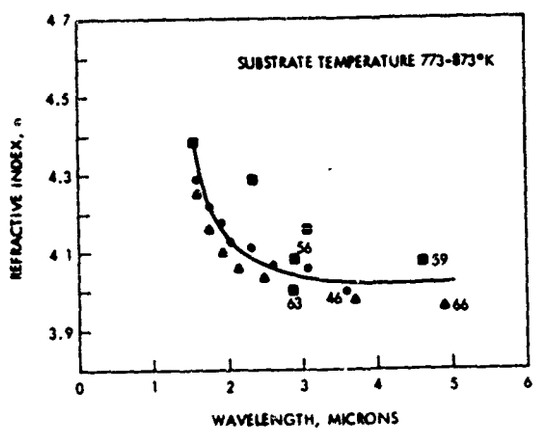
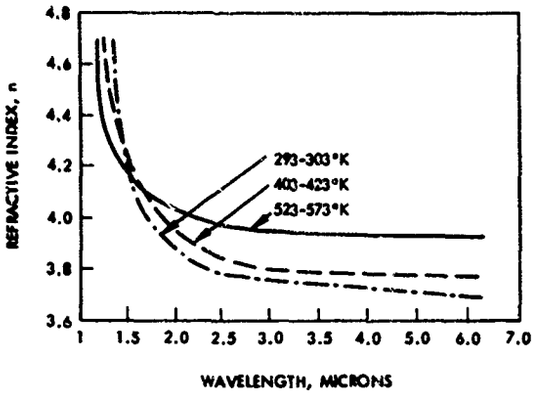



Figure 5-69

(773 - 873° K)

PARAMETER: Film Deposition Substrate Temperature




MATERIAL: Germanium

FORM Film, amorphous and polycrystalline

THICKNESS $\sim 1 \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.25 - 6.5 μ

TEMPERATURE $\sim 298$ °K

METHOD Interference

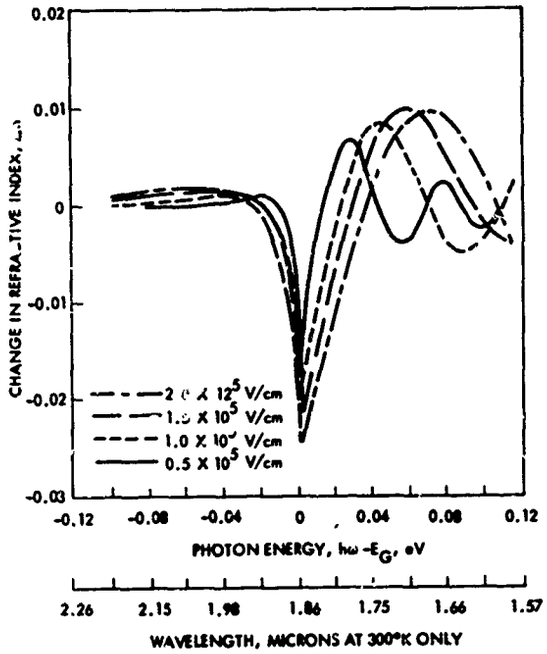
REFERENCE Gisin and Ivanov (41222 )

REMARKS Evaporation of single crystal germanium of resistivity = 40 ohm-cm from graphite boat onto barium fluoride substrate at $(2\text{-}5) \times 10^{-5}$ Torr pressure.

Figure 5-70

**PARAMETER:** Electric Field

**MATERIAL:** Germanium




**FORM** Single Crystal pn Junction

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.6 - 2.2 μ

**TEMPERATURE** 300 °K

**METHOD** Reflection

**REFERENCE** Seraphin and Bottka (38093)

**REMARKS** Wavelength is based on energy gap data from McFarlane, et al. (184).

Figure 5-71

## ZINC SULFIDE

### INTRODUCTION

Zinc sulfide occurs in two crystal forms: cubic (zincblende or sphalerite) and hexagonal (wurtzite). This semiconducting material is used in infrared optics and in luminescent devices. Single crystals for optical applications have been grown by the static vapor growth method in which powdered zinc sulfide is kept in the high temperature region. The powdered zinc sulfide is usually prepared by precipitation from aqueous solution. Highly purified zinc sulfide has a resistivity of approximately $5 \times 10^7$ ohm-cm for the hexagonal form, measured in darkness.

The physical properties of intrinsic zinc sulfide were summarized in Table 1-1. A more complete compilation of properties is offered in Report No. S-11. Figure 1-9 shows the infrared transmission by zinc sulfide.

### DATA

The data for zinc sulfide are listed in Table 5-19 and the wavelength coverage in Table 5-20. The data cover hexagonal, cubic, amorphous, and a mixture of cubic and hexagonal zinc sulfide. No data at temperatures other than room temperature were located.

Refractive index data for hexagonal zinc sulfide, single crystal material, are presented in Figures 5-72 to 5-73 and Tables 5-21 to 5-22; sinc hexagonal zinc sulfide is birefringent, plots for ordinary and extraordinary rays are included. Cubic crystal data are shown in Figures 5-74 to 5-77 and Tables 5-23 to 5-25. Figure 5-78 and Table 5-26 present data for Irtran-2, a polycrystalline material composed of 95 percent cubic and 5 percent hexagonal material Film data are provided in Figures 5-79 to 5-82 and in Table 5-27. The dependence

PRECEDING PAGE BLANK

of the refractive index on zinc sulfide content has been demonstrated for a germanium/zinc sulfide film in Figure 5-58.

No significant difference is observed between the bulk data for the ordinary ray on hexagonal zinc sulfide and for cubic zinc sulfide. Films tend to have a lower refractive index than bulk material.

Table 5-19. List of Zinc Sulfide Data

| Figure | Table | n or k | Form | Crystal | Wavelength (Microns) From | Wavelength (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-72 | | n | Bulk | Single | 0.6 | 1.4 | Hexagonal | Wavelength |
| | 5-21 | n | Bulk | Single | 0.6 | 1.4 | Hexagonal | Wavelength |
| 5-73 | | n | Bulk | Single | 0.3 | 1.6 | Hexagonal | Wavelength |
| | 5-22 | n | Bulk | Single | 4.0 | 15.0 | Hexagonal | Wavelength |
| 5-74 | | n | Bulk | Single | 0.8 | 1.4 | Cubic | Wavelength |
| | 5-23 | n | Bulk | Single | 0.7 | 1.4 | Cubic | Wavelength |
| 5-75 | | n | Bulk | Single | 0.3 | 4.0 | Cubic | Wavelength |
| | 5-24 | n | Bulk | Single | 0.7 | 4.0 | Cubic | Wavelength |
| | 5-25 | n | Bulk | * | 0.8 | 2.4 | Cubic | Wavelength |
| 5-76 | | n, k | Bulk | * | 20 | 70 | Cubic | Wavelength |
| 5-77 | | n | Bulk | * | 0.7 | 1.5 | Cubic | Wavelength |
| 5-78 | | n | Bulk | Polycryst** | 1.0 | 14.0 | | Wavelength |
| | 5-26 | n | Bulk | Polycryst** | 1.0 | 13.0 | | Wavelength |
| 5-79 | | n | Film | Amorphous | 0.75 | 2.0 | | Wavelength |
| 5-80 | | n | Film | Amorphous | 2.0 | 14.0 | | Wavelength |
| 5-81 | | n | Film | * | 0.4 | 1.2 | | Wavelength |
| 5-82 | | n | Film | * | 0.8 | 3.2 | | Wavelength |
| | 5-27 | n | Film | * | 0.74 | 1.0 | | Wavelength |

*Not stated

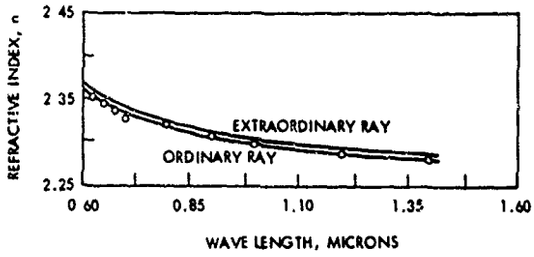
**95 percent cubic, 5 percent hexagonal (IRTRAN-2, product of Eastman-Kodak Co.)

Table 5-20. Range of Refractive Index Data for Zinc Sulfide (300°K)

| Material | Range in Wavelength, Microns From | To | From | To |
|---|---|---|---|---|
| Bulk, cubic | 0.3 | 4.0 | 20 | 70 |
| Bulk, hexagonal | 0.3 | 1.6 | 4 | 15 |
| Bulk, polycryst. | 1.0 | 13 | | |
| Film, amorphous | 0.8 | 14 | | |

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide




FORM Bulk, Single Crystal, Hexagonal

THICKNESS NA (prism) mm

RAY ORDINARY ☐, EXTRAORDINARY ☒

WAVELENGTH 0.6 - 1.4 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE Bieniewsky & Czyzak(8761)

REMARKS

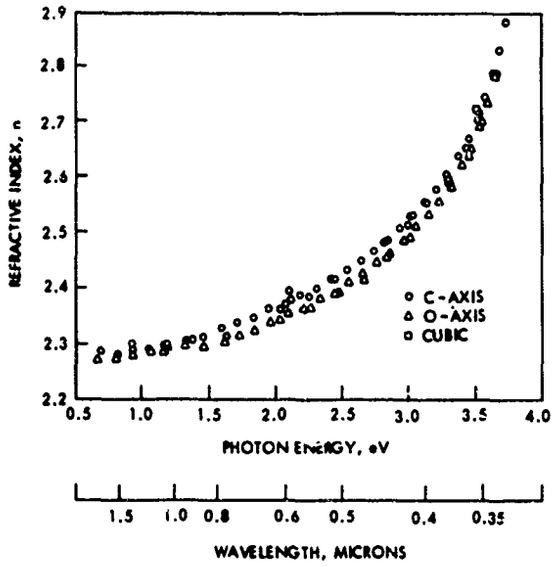
Figure 5-72

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | Extraordinary Ray | Ordinary Ray |
| 0.600 | 2.368 | 2.363 |
| 6.625 | 2.358 | 2.354 |
| 0.6500 | 2.350 | 2.346 |
| 0.6750 | 2.343 | 2.339 |
| 0.7000 | 2.337 | 2.332 |
| 0.8000 | 2.328 | 2.324 |
| 0.9000 | 2.315 | 2.310 |
| 1.0000 | 2.303 | 2.301 |
| 1.2000 | 2.294 | 2.290 |
| 1.4000 | 2.288 | 2.285 |

Table 5-21

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide




FORM Bulk, Single Crystal, Hexagonal

THICKNESS $5 \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☒

WAVELENGTH 0.3 - 1.6; 4 - 15 μ

TEMPERATURE 293 °K

METHOD Interference

REFERENCE Piper, et al. (735)

REMARKS

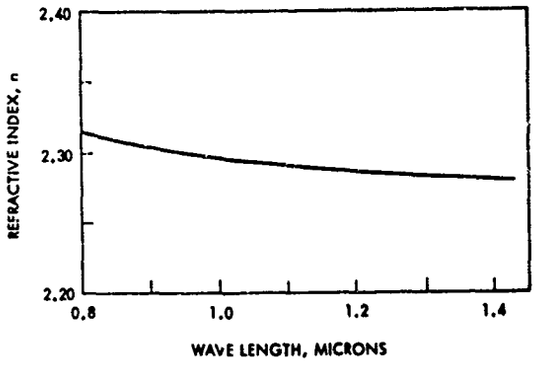
Figure 5-73

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 4 - 15 | 2.26 ± 0.06 |

Table 5-22

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide




FORM Bulk, Single Crystal, Cubic mm

THICKNESS NA (prism)

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.7 - 1.4 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE Czyzak, et al. (6331)

REMARKS

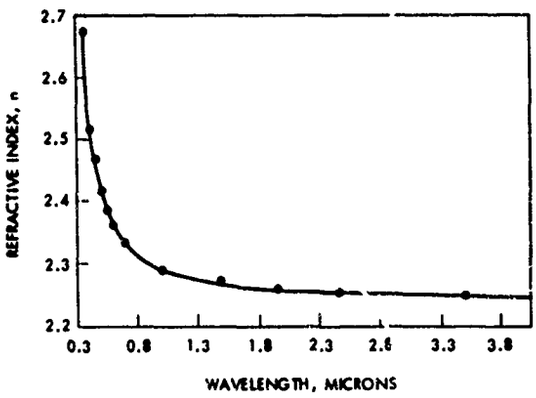
Figure 5-74

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | Calculated | Observed |
| 0.700 | 2.332 | 2.334 |
| 0.900 | 2.303 | 2.306 |
| 1.050 | 2.293 | 2.293 |
| 1.200 | 2.285 | 2.282 |
| 1.400 | 2.280 | 2.284 |

Table 5-23

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide




FORM Bulk, Single Crystal, Cubic mm

THICKNESS NA (Prism)

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.3 - 4.0 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE Czyzak, et al. (14914)

REMARKS

Figure 5-75

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | Calculated | Measured |
| 0.700 | 2.329 | 2.332 |
| 1.000 | 2.292 | 2.293 |
| 1.500 | 2.270 | 2.275 |
| 2.000 | 2.260 | 2.263 |
| 2.500 | 2.256 | 2.256 |
| 3.000 | 2.253 | 2.253 |
| 3.500 | 2.251 | 2.251 |
| 4.000 | 2.250 | 2.251 |

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.7 - 4.0 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE Czyzak, et al. (14914)

REMARKS

Table 5-24

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.8 | 2.3146 |
| 0.9 | 2.3026 |
| 1.0 | 2.2932 |
| 1.2 | 2.2822 |
| 1.4 | 2.2762 |
| 1.6 | 2.2716 |
| 1.8 | 2.2680 |
| 2.0 | 2.2653 |
| 2.2 | 2.2637 |
| 2.4 | 2.2604 |

FORM Bulk, Cubic mm

THICKNESS NA (Prism)

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 2.4 μ

TEMPERATURE ~298 °K

METHOD Deviation

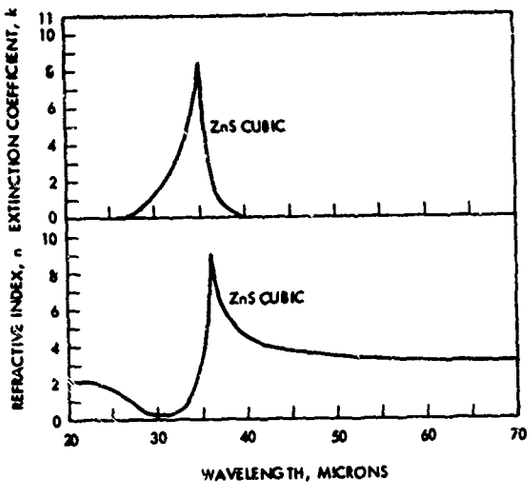
REFERENCE Bond (19989)

REMARKS Natural crystal from Spain

Table 5-25

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide




FORM Bulk, Cubic

THICKNESS Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 20 - 70 μ

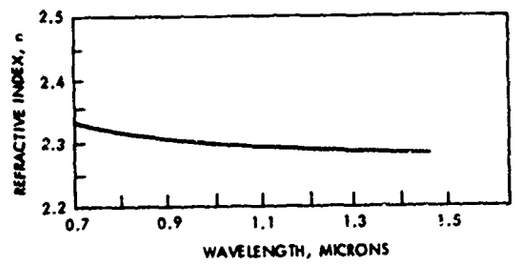
TEMPERATURE 300 °K

METHOD Reflection

REFERENCE Manabe (28526)

REMARKS Natural crystal

Figure 5-76




THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.7 - 1.5 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE DeVore (40276)

REMARKS Sphalerite, natural crystal

Figure 5-77

**PARAMETER:** Wavelength

**MATERIAL:** Zinc Sulfide

**FORM** Bulk, Polycrystalline

**THICKNESS** Not Stated mm

**RAY** ORDINARY ☒ , EXTRAORDINARY ☐

**WAVELENGTH** 1.0 - 14.0 μ

**TEMPERATURE** ~298 °K

**METHOD** Not Stated

**REFERENCE** Kodak [1967]

**REMARKS** IRTRAN-2 material

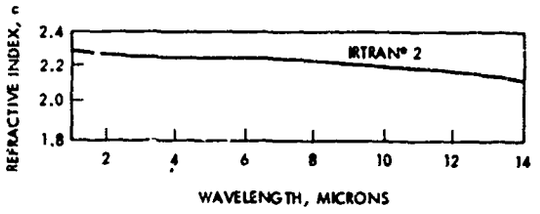



Figure 5-78

| Wavelength, (Microns) | Refractive Index n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.0000 | 2.2907 | 6.0000 | 2.2381 |
| 1.2500 | 2.2777 | 6.2500 | 2.2363 |
| 1.5000 | 2.2706 | 6.5000 | 2.2344 |
| 1.7500 | 2.2662 | 6.7500 | 2.2324 |
| 2.0000 | 2.2631 | 7.0000 | 2.2304 |
| 2.2500 | 2.2608 | 7.2500 | 2.2282 |
| 2.5000 | 2.2589 | 7.5000 | 2.2260 |
| 2.7500 | 2.2573 | 7.7500 | 2.2237 |
| 3.0000 | 2.2558 | 8.0000 | 2.2213 |
| 3.2500 | 2.2544 | 8.2500 | 2.2188 |
| 3.5000 | 2.2531 | 8.5000 | 2.2162 |
| 3.7500 | 2.2518 | 8.7500 | 2.2135 |
| 4.0000 | 2.2504 | 9.0000 | 2.2107 |
| 4.2500 | 2.2491 | 9.2500 | 2.2078 |
| 4.5000 | 2.2477 | 9.5000 | 2.2048 |
| 4.7500 | 2.2462 | 9.7500 | 2.2018 |
| 5.0000 | 2.2447 | 10.0000 | 2.1986 |
| 5.2500 | 2.2432 | 11.0000 | 2.1846 |
| 5.5000 | 2.2416 | 12.0000 | 2.1688 |
| 5.7500 | 2.2399 | 13.0000 | 2.1508 |

Table 5-26

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide

FORM Film, Amorphous

THICKNESS (1-4) x $10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.75 - 14 μ

TEMPERATURE ~298 °K

METHOD Transmission, Reflection

REFERENCE Hall & Ferguson (2609)

REMARKS Vapor-deposited film-
0.75 - 2 micron data on glass substrate, 2 - 14 microns on rock salt substrate

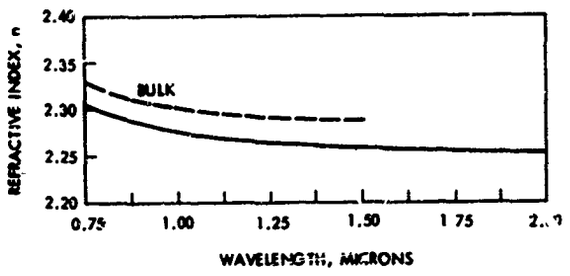



Figure 5-79

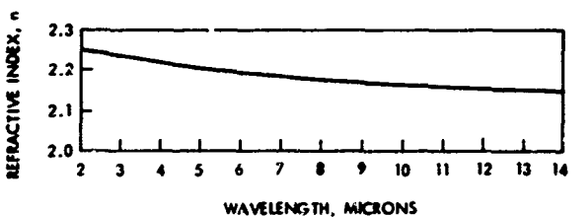
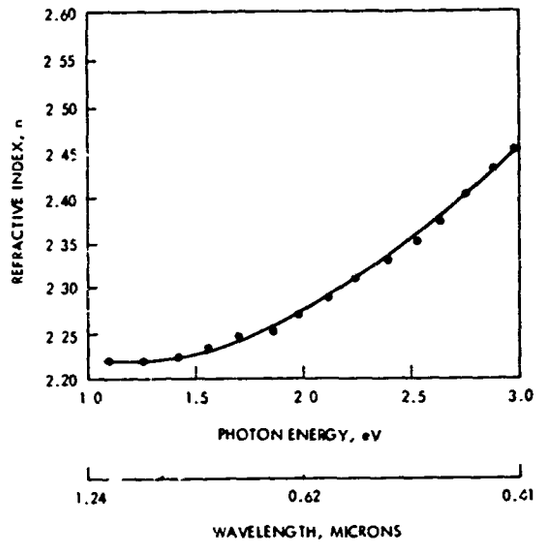



Figure 5-80

**PARAMETER:** Wavelength

**MATERIAL:** Zinc Sulfide




**FORM** Film

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.4 - 1.2 μ

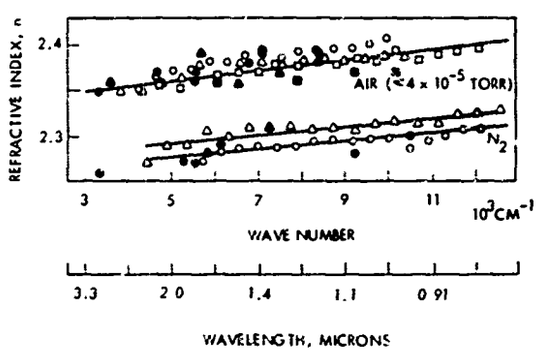
**TEMPERATURE** ~298 °K

**METHOD** Interference

**REFERENCE** Burgiel, et al. (34617)

**REMARKS** Sputtered and evaporated films used with identical results. Sputtered film was predominantly cubic.

Figure 5-81




Air plots: O, layer with d = 2.500μ, Δ, d = 2.221μ; ☐, d = 2.258μ. Nitrogen plots: O, layer with d = 2.501μ, Δ, d = 2.233μ. + determined by calculation. x determined from Brewster angle; remaining plots from geometrical thickness of film.

**THICKNESS** $2.5 \times 10^{-3}$ mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.8 - 3.2 μ

**TEMPERATURE** ~298 °K

**METHOD** Interference

**REFERENCE** Huldt & Staflin (3735)

**REMARKS** Evaporation onto glass substrate in atmosphere of air or nitrogen.

Figure 5-82

PARAMETER: Wavelength

MATERIAL: Zinc Sulfide

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.740 | 2.30 | 0.000 |
| 0.900 | 2.23 | 0.000 |
| 0.980 | 2.27 | 0.000 |

FORM Film

THICKNESS $3 \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.74 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Trarsmission, Reflection

REFERENCE Kuwabara & Isiguro (40442)

REMARKS Film evaporated onto glass substrate at $\sim 10^{-4}$ Torr.

Table 5-27

## CADMIUM TELLURIDE

### INTRODUCTION

Cadmium telluride is a semiconductor that has found application in infrared optics and semiconductor devices including solar cells. This material may show both n- and p type conduction; addition of excess cadmium gives n-type conduction and conversely, addition of excess tellurium gives p-type conduction.

Cadmium telluride is usually prepared from electrolytic cadmium and vacuum-distilled tellurium by direct combination at an elevated temperature under a nitrogen atmosphere. Zone refining is used for further purification. The electrical and optical properties are strongly affected by deviation from the stochiometric ratio of the components (cadmium and tellurium). Details concerning the equilibrium phase diagram for cadmium telluride may be located in EPIC Data Sheet DS-157. The electrical resistivity of highly pure single crystal cadmium telluride at room temperature is approximately $10^7$ ohm-cm. The optical transmission by cadmium telluride is shown in Figures 1-9 and 1-10.

The physical properties of cadmium telluride were summarized in Table 1-1.

EPIC Report S-11 provides additional property data on cadmium telluride. As with other semiconductors, different doping levels in authors' reports make it often difficult to compare their results.

### DATA

All data presentations for cadmium telluride are listed in Table 5-28 and a summary of wavelength and temperature coverage is plotted in Figure 5-83. Figures 5-84 to Figure 5-88 and Tables 5-29 to 5-31 represent refractive index spectra for bulk single crystal material. Below five microns, the pure or lightly n-doped materials show no wide differences in refractive index. At longer wavelengths the data exhibit a far wider spread between the author's data and it

would be difficult to recommend a "best" set of values. Heavily n-doped materials are represented by data in Figures 5-89, 5-90 and 5-91. The data in Tables 5-32 to 5-34 and Figure 5-90 and 5-91, could not be identified regarding their crystalline status (e.g., single crystal) but, except for heavily doped materials, they show no marked departure from the spread for single crystals.

Figures 5-92 to 5-95 and Tables 5-35 to 5-37 cover polycrystalline materials and the data are similar to those obtained from single crystal material of a similar doping level.

The temperature dependence of the refractive index is the subject of Tables 5-38 to 5-39 and Figures 5-96 to 5-101. The relative sparsity of such data does not permit any generalization.

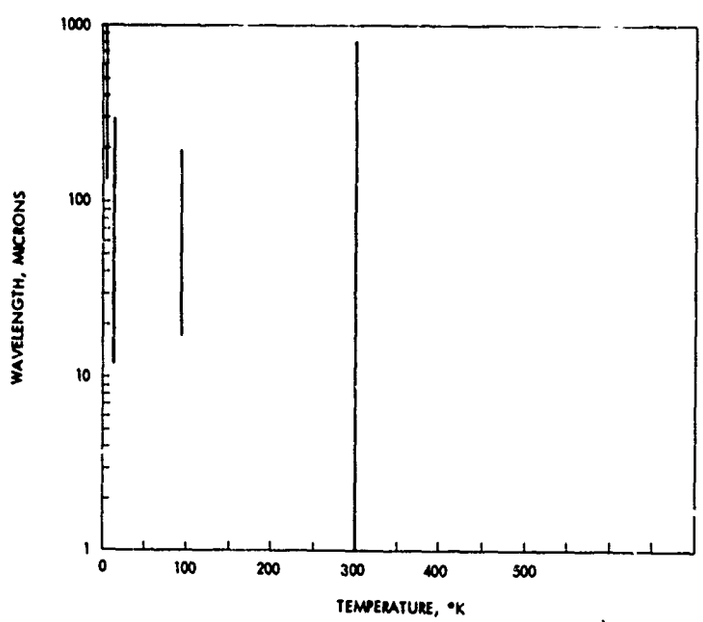



Figure 5-83. Wavelength and Temperature Range for Cadmium Telluride Data

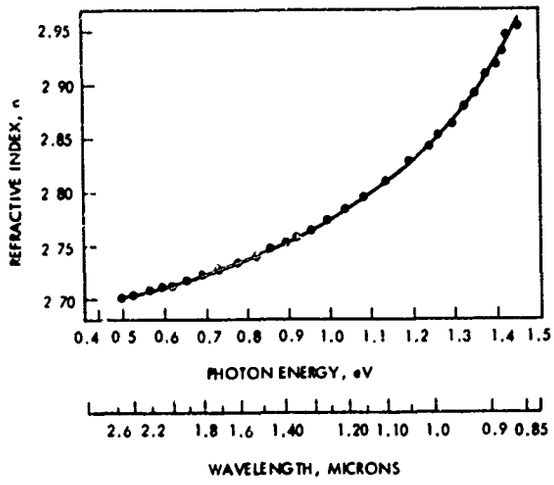
## Table 5-28. List of Cadmium Telluride Data

| Figure | Table | n or k | Form | Crystal | Wavelength, (Microns) From | Wavelength, (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-84 | | n | Bulk | Single | 0.085 | 2.6 | | Wavelength |
| | 5-29 | n | Bulk | Single | 2.0 | 10.0 | | Wavelength |
| 5-85 | | n | Bulk | Single | 12.5 | 300 | 8, 300°K | Wavelength |
| 5-86 | | n | Bulk | Single | 133 | 1000 | 4.2°K | Wavelength |
| 5-87 | | n, k | Bulk | Single | 37 | 85 | 100, 300°K | Wavelength |
| 5-88 | | n | Bulk | Single | 5.0 | 10.0 | | Wavelength |
| | 5-30 | n | Bulk | Single | 0.87 | 1.00 | n-type 293°, 373°K | Wavelength |
| 5-89 | | n | Bulk | Single | 6.5 | 14.5 | n-type, heavily doped | Wavelength |
| | 5-31 | n | Bulk | Single | 0.90 | 1.1 | n-type | Wavelength |
| | 5-32 | n | Bulk | * | 2.5 | 2.5 | n-type | Wavelength |
| | 5-33 | n | Bulk | * | 8.0 | 14.0 | n-type | Wavelength |
| | 5-34 | n | Bulk | * | 10.0 | 10.0 | n-type | Wavelength |
| 5-90 | | n, k | Bulk | * | 20 | 200 | n-type, heavily doped 100°K | Wavelength |
| 5-91 | | n, k | Bulk | * | 20 | 200 | n-type, heavily doped 300°K | Wavelength |
| 5-92 | | n | Bulk | Polycryst. | 1.0 | 16.0 | | Wavelength |
| | 5-35 | n | Bulk | Polycryst. | 1.0 | 16.0 | | Wavelength |
| 5-93 | | n, k | Bulk | Polycryst. | 50 | 75 | 90°K | Wavelength |
| 5-94 | | n, k | Bulk | Polycryst | 55 | 78 | 300°K | Wavelength |
| 5-95 | | n | Bulk | Polycryst. | 220 | 1000 | | Wavelength |
| | 5-36 | n | Bulk | Polycryst. | 1.0 | 10.0 | | Wavelength |
| | 5-37 | n | Bulk | Polycryst. | 23 | 28 | n-type | Wavelength |
| | 5-38 | n | Bulk | Single | 0.87 | 1.00 | n-type, 293, 373°K | Temperature |
| 5-96 | | n | Bulk | Single | 37 | 85 | 100, 300°K | Temperature |
| 5-97 | | n | Bulk | * | 20 | 200 | n-type, 100°K | Temperature |
| 5-98 | | n | Bulk | * | 20 | 200 | n-type, 300°K | Temperature |
| 5-99 | | n | Bulk | * | 12.5 | 300 | 8°, 300°K | Temperature |
| 5-100 | | n | Bulk | Polycryst. | 50 | 75 | 90°K | Temperature |
| 5-101 | | n | Bulk | Polycryst. | 55 | 78 | 300°K | Temperature |
| | 5-39 | $1/n(\frac{dn}{dT})$ | Bulk | Single | 10.6 | 10.6 | 293 - 318°K | Temperature |

*Not Stated

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.085 - 2.6 μ

TEMPERATURE ~298 °K

METHOD Deviation

REFERENCE Marple (15085)

REMARKS Material grown from melt containing < 10 ppm total impurities.

Figure 5-84

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 2.0 | 2.710 |
| 3.0 | 2.694 |
| 4.0 | 2.687 |
| 5.0 | 2.680 |
| 6.0 | 2.675 |
| 8.0 | 2.669 |
| 10.0 | 2.658 |

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 10 μ

TEMPERATURE ~298 °K

METHOD Deviation

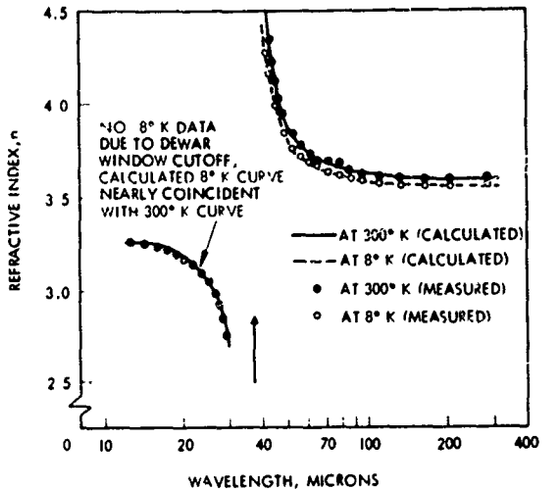
REFERENCE Vitrikhovskiy (31017)

REMARKS

Table 5-29

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk

THICKNESS 0.172 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 12.5 - 300 μ

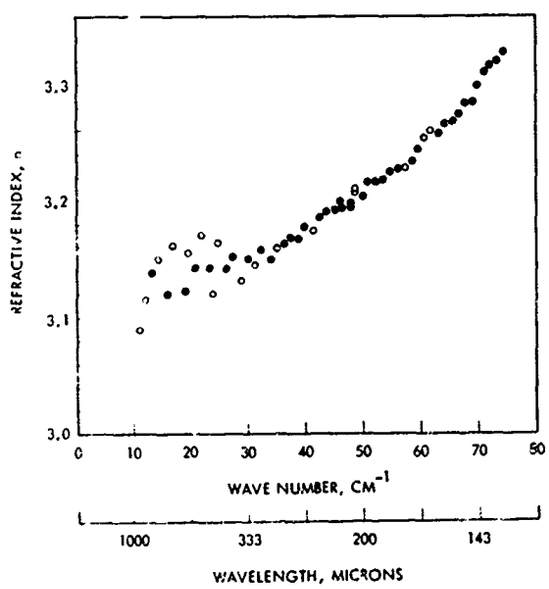
TEMPERATURE 8, 300 °K

METHOD Interference

REFERENCE Johnson, et al. (40781)

REMARKS Resistivity = $8.5 \times 10^5$ ohm-cm.

Figure 5-85




THICKNESS 1.22 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 133 - 100 μ

TEMPERATURE 4.2 °K

METHOD Interference

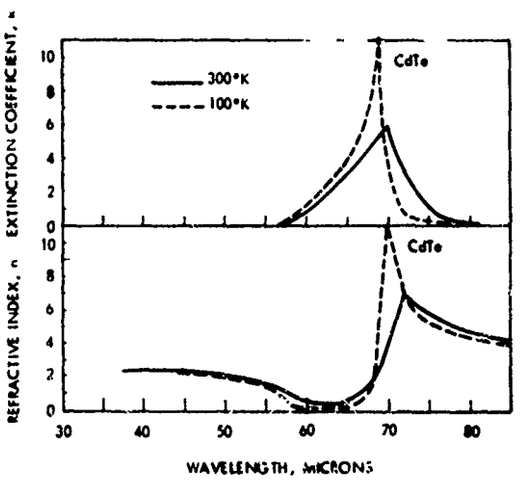
REFERENCE Halsted, et al. (26678)

REMARKS

Figure 5-86.

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 37 - 85 μ

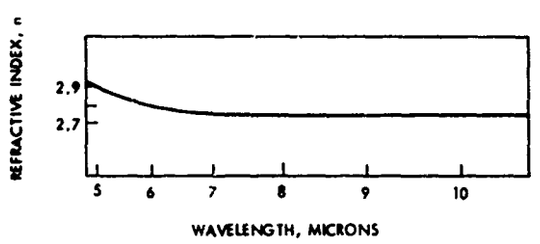
TEMPERATURE 100, 300 °K

METHOD Reflection

REFERENCE Manabe, et al. (28526)

REMARKS

Figure 5-87




THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 5 - 10 μ

TEMPERATURE 300 °K

METHOD Reflection

REFERENCE De Nobel (306)

REMARKS

Figure 5-88

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride

| Temperature, °K | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|
| 293 | 0.865 | 3.50 max. |
| 293 | 0.900 | 3.20 |
| 293 | 1.000 | 2.80 |
| 373 | 0.872 | 3.40 max. |
| 373 | 0.900 | 3.15 |
| 373 | 1.000 | 3.20 |

FORM Bulk, Single Crystal

THICKNESS 0.1 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.87 - 1.00 μ

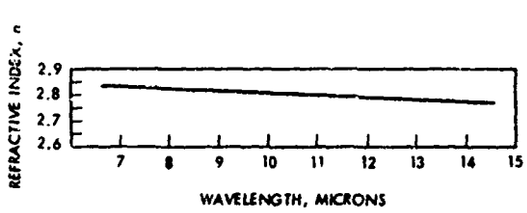
TEMPERATURE ~298 °K

METHOD Reflection, Transmission

REFERENCE Konak (11590)

REMARKS n-type material, resistivity $\approx 10^5$ ohm-cm

Table 5-30




THICKNESS 0.63, 1.10 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 6.5 - 14.5 μ

TEMPERATURE ~298 °K

METHOD Reflection

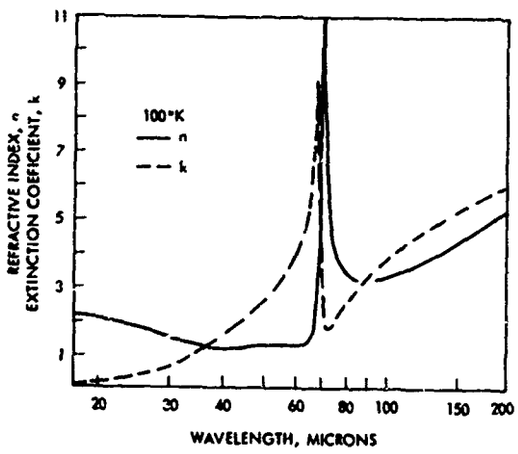
REFERENCE Planker & Kauer (40526)

REMARKS n-type material, Gallium concentration $\sim 5 \times 10^{17}$ $cm^{-3}$

Figure 5-89

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 20 - 200 μ

TEMPERATURE 100, 300 °K

METHOD Reflection

REFERENCE Manabe, et al. (36435)

REMARKS n-type material, indium-doped, carrier concentration = $5.25 \times 10^{17}$ $cm^{-3}$ at 300°K, resistivity = $1.92 \times 10^{-2}$ ohm-cm at 300°K.

Figure 5-90

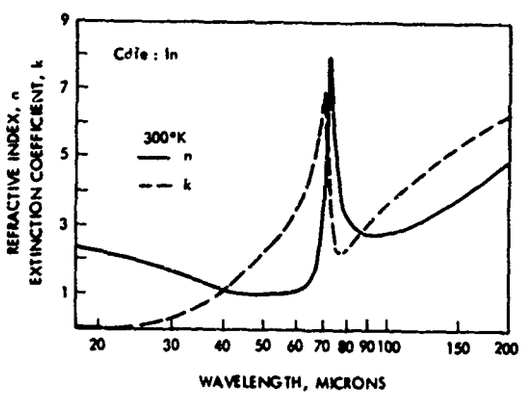



Figure 5-91

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.903 | 3.47 ± 0.05 |
| 1.100 | 3.13 ± 0.04 |

FORM Bulk, single crystal

THICKNESS 1.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.90, 1.10 μ

TEMPERATURE ~298 °K

METHOD Not stated

REFERENCE Garlick, et al. (7771)

REMARKS n-type, indium-doped, concentration not stated.

Table 5-31

| Wavelength, Microns | Refractive Index, n |
|---|---|
| 2.5 | 2.70 |

THICKNESS 4.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.5 μ

TEMPERATURE ~298 °K

METHOD Reflectance

REFERENCE Marple (10559)

REMARKS Pure n-type material with carrier concentration $= 6 \times 10^{14}$ $cm^{-3}$

Table 5-32

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 8-14 | 2.67 |

FORM Bulk

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 8 - 14 μ

TEMPERATURE 298 °K

METHOD Interference

REFERENCE Fisher & Fan (5400)

REMARKS n-type material with electron concentration ~ $1 \times 10^{15}$ $cm^{-3}$

Table 5-33

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 10 | 2.61 |

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 10 μ

TEMPERATURE ~298 °K

METHOD Interference

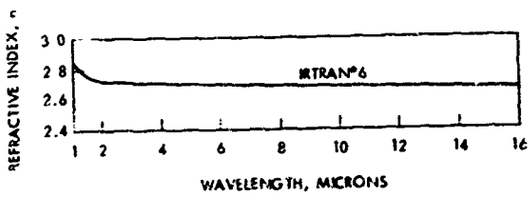
REFERENCE Davis & Shilliday (3648)

REMARKS Pure n-type material with carrier concentration ~$1 \times 10^{15}$ $cm^{-3}$

Table 5-34

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk, polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 1.0 - 16 μ

TEMPERATURE 298 °K

METHOD Not stated

REFERENCE Kodak (1967)

REMARKS

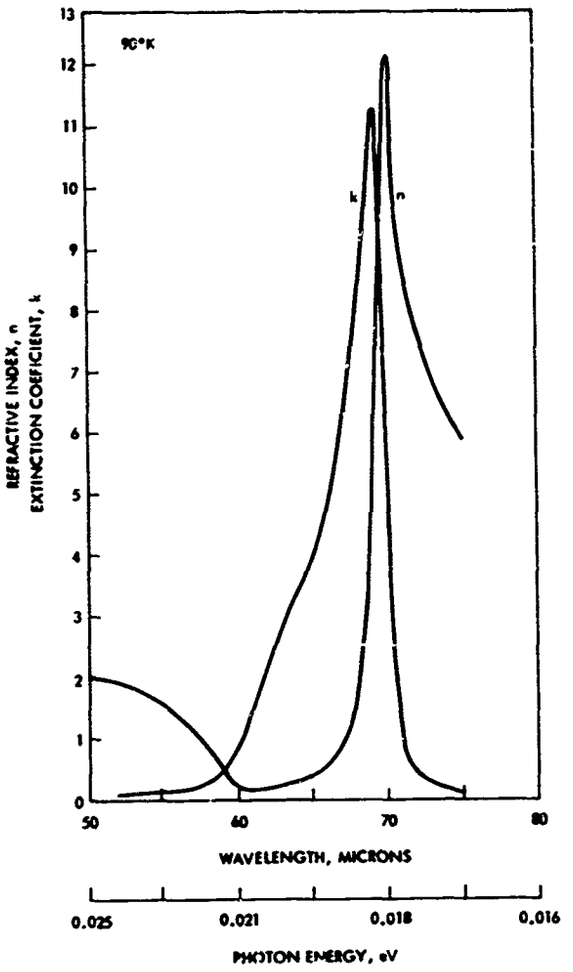
Figure 5-92

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.0000 | 2.838 | 6.2500 | 2.681 |
| 1.2500 | 2.773 | 6.5000 | 2.680 |
| 1.5000 | 2.742 | 6.7500 | 2.680 |
| 1.7500 | 2.725 | 7.0000 | 2.679 |
| 2.0000 | 2.714 | 7.2500 | 2.678 |
| 2.2500 | 2.707 | 7.5000 | 2.678 |
| 2.5000 | 2.702 | 7.7500 | 2.677 |
| 2.7500 | 2.698 | 8.0000 | 2.677 |
| 3.0000 | 2.695 | 8.2500 | 2.676 |
| 3.2500 | 2.693 | 8.5000 | 2.675 |
| 3.5000 | 2.691 | 8.7500 | 2.675 |
| 3.7500 | 2.689 | 9.0000 | 2.674 |
| 4.0000 | 2.688 | 9.2500 | 2.674 |
| 4.2500 | 2.687 | 9.5000 | 2.673 |
| 4.5000 | 2.686 | 9.7500 | 2.672 |
| 4.7500 | 2.685 | 10.0000 | 2.672 |
| 5.0000 | 2.684 | 11.0000 | 2.669 |
| 5.2500 | 2.683 | 12.0000 | 2.666 |
| 5.5000 | 2.683 | 13.0000 | 2.663 |
| 5.7500 | 2.682 | 14.0000 | 2.660 |
| 6.0000 | 2.681 | 15.0000 | 2.657 |
| | | 16.0000 | 2.655 |

Table 5-35

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk, Polycrystalline mm

THICKNESS Not stated

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 50 - 78 μ

TEMPERATURE 90, 300 °K

METHOD Reflection

REFERENCE Mitsuishi (481)

REMARKS

Figure 5-93

PARAMETER: Wavelength (Cont' d from preceding page) MATERIAL: Cadmium Telluride

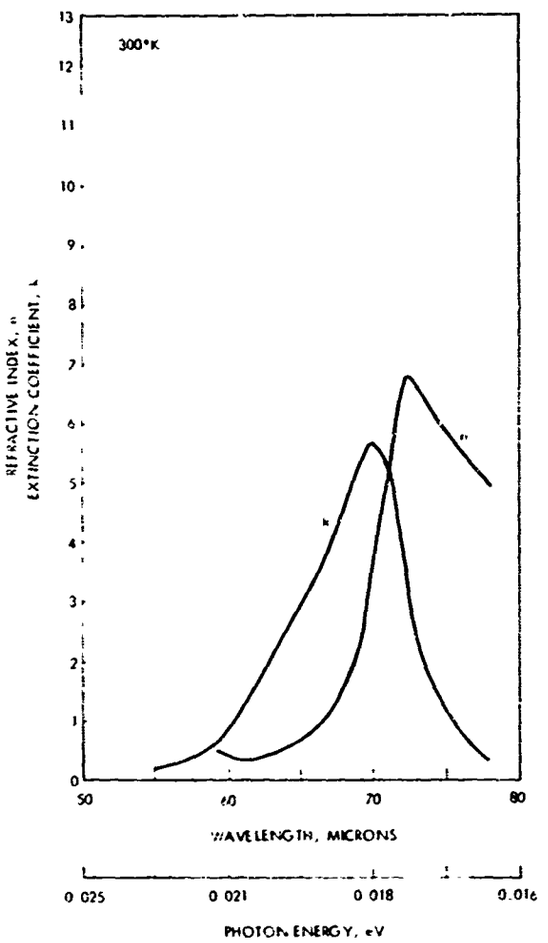



Figure 5-94

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride

FORM Bulk, polycrystalline

THICKNESS 1 - 3 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 23.3 - 28 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Lorimor & Spitzer (20784)

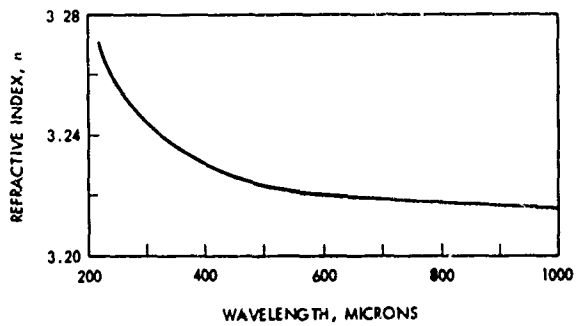
REMARKS Pure, n-type with carrier concentration ~ $1 \times 10^{15}$ $cm^{-3}$ at 298°K

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 23.35 | 2.58 |
| 27.95 | 2.53 |

Table 5-37

PARAMETER: Wavelength

MATERIAL: Cadmium Telluride




FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 220 - 1000 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Randall & Rawcliffe(33290)

REMARKS IRTRAN-6 material

Figure 5-95

| Wavelength, (Microns) | Refractive index, n |
|---|---|
| 1.0 | 2.839 |
| 1.5 | 2.742 |
| 2.0 | 2.713 |
| 2.5 | 2.702 |
| 3.0 | 2.695 |
| 3.5 | 2.691 |
| 4.0 | 2.688 |
| 5.0 | 2.684 |
| 6.0 | 2.681 |
| 7.0 | 2.679 |
| 8.0 | 2.677 |
| 9.0 | 2.674 |
| 10.0 | 2.672 |

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 10 μ

TEMPERATURE 298 °K

METHOD Deviation

REFERENCE Ladd (27063)

REMARKS ITRAN-6 material

Table 5-36

PARAMETER: Temperature

MATERIAL: Cadmium Telluride

| Temperature, °K | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|
| 293 | 0.865 | 3.50 max. |
| 293 | 0.900 | 3.20 |
| 293 | 1.000 | 2.80 |
| 373 | 0.872 | 3.40 max. |
| 373 | 0.900 | 3.15 |
| 373 | 1.000 | 3.20 |

FORM Bulk, Single Crystal

THICKNESS 0.1 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.87 - 1.00 μ

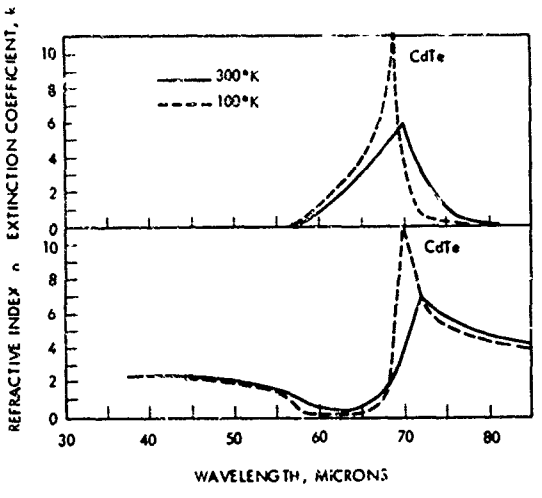
TEMPERATURE ~298 °K

METHOD Reflection, Transmission

REFERENCE Konak (11590)

REMARKS n-type material, resistivity ≅ $10^5$ ohm-cm

Table 5-38




THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 37 - 85 μ

TEMPERATURE 100, 300 °K

METHOD Reflection

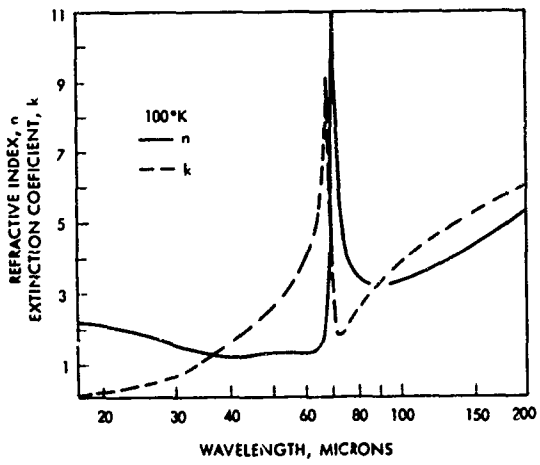
REFERENCE Manabe, et al (28526)

REMARKS

Figure 5-96

PARAMETER: Temperature

MATERIAL: Cadmuim Telluride




FORM Bulk

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 20 - 200 μ

TEMPERATURE 100, 300 °K

METHOD Reflection

REFERENCE Manabe, et al. (36435)

REMARKS n-type material, indium-doped, carrier concentration = $5.25 \times 10^{17}$ $cm^{-3}$ at 300°K, resistivity = $1.92 \times 10^{-2}$ ohm-cm at 300°K.

Figure 5-97

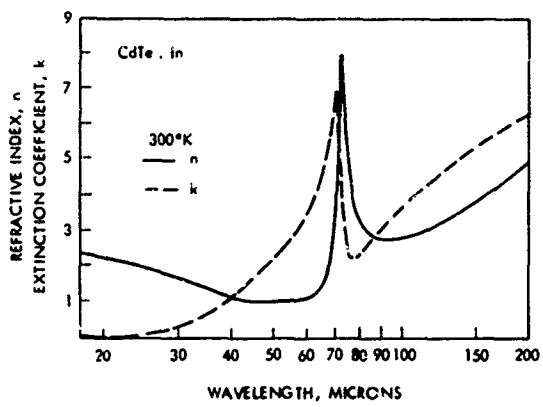
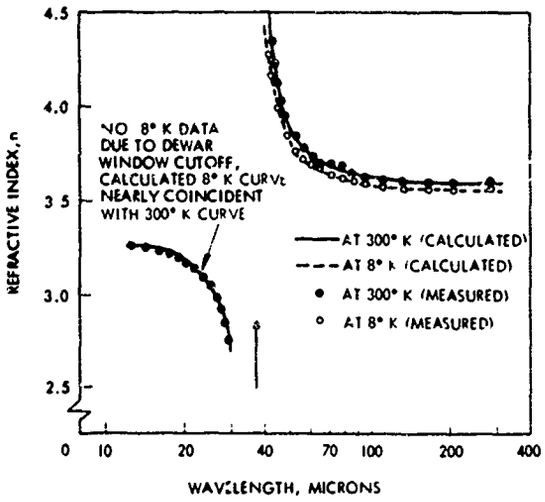



Figure 5-98

**PARAMETER:** Temperature

**MATERIAL:** Cadmium Telluride




**FORM** Bulk

**THICKNESS** 0.172 mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 12.5 - 300 μ

**TEMPERATURE** 8, 300 °K

**METHOD** Interference

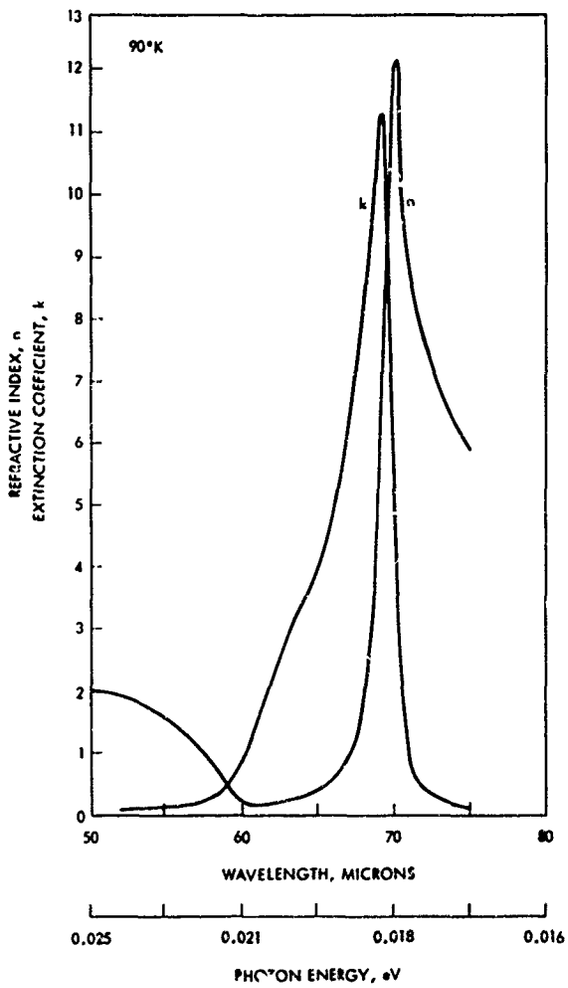
**REFERENCE** Johnson, et al. (40781)

**REMARKS** Resistivity = $8.5 \times 10^5$ ohm-cm

Figure 5-99

PARAMETER: Temperature

MATERIAL: Cadmium Telluride




FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 50 - 78 μ

TEMPERATURE 90, 300 °K

METHOD Reflection

REFERENCE Mitsuishi (481)

REMARKS

Figure 5-100

**PARAMETER:** Temperature (Cont'd from preceding page) **MATERIAL:** Cadmium Telluride

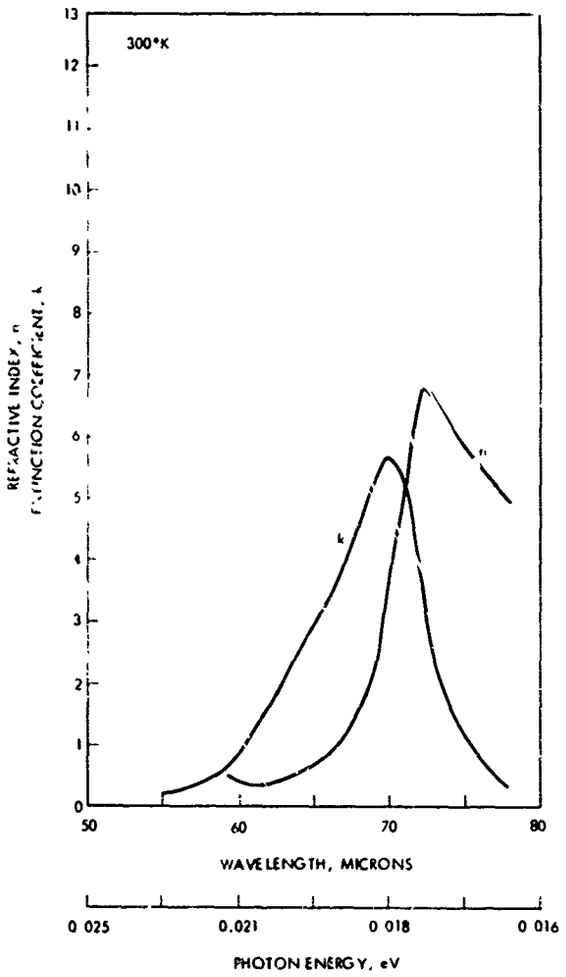



Figure 5-101

PARAMETER: Temperature

MATERIAL: Cadmium Telluride

FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 10.6 μ

TEMPERATURE 293 - 318 °K

METHOD Interference

REFERENCE Weil & Johnson (41152)

REMARKS

$$(1/n)(dn/dT) = (4.02 \pm 0.05)\times10^{-5}\ (°K)^{-1}$$

Table 5-39

## ZINC SELENIDE

### INTRODUCTION

Zinc selenide is a semiconductor that has found application in infrared optics and in cathodoluminescence. Zinc selenide is a relatively new material and no generally recommended preparation method appears to have evolved thus far. Preparation methods include the direct preparation from the elements (Zn + Se) under argon and the reduction of a solution of zinc selenite hydrazine with subsequent decomposition of the precipitated hydrazine complex by addition of acetic acid. Typical crystal growth methods use zinc selenide powder as starting material for the growth of single crystals.

Zinc selenide transmits infrared light to a wavelength of eighteen microns as shown in Figure 1-9. Evaporated films of zinc selenide have a resistivity of $10^8$ to $10^9$ ohm-cm at $300^oK$. The physical properties of zinc selenide were summarized in Table 1-1 and are given in greater detail in EPIC Report S-11.

### DATA

All data presentations for zinc selenide are listed in Table 5-40 and a summary of wavelength and temperature coverage is plotted in Figure 5-102. Refractive index data as a function of wavelength are shown in Figures 5-103 to 5-111 and Tables 5-41 to 5-42. The data agree quite well with one another from one to twenty microns, but at longer wavelengths the data are rather scattered. The only single crystal result agrees fairly well with polycrystalline data over the range from 1.0 to 1.8 microns. The zinc selenide compilations also include a number of plots of extinction coefficient measurements. The temperature dependence of the refractive index and the extinction coefficient is the subject of Figures 5-112 to 5-118.

PRECEDING PAGE BLANK

Table 5-40. List of Zinc Selenide Data

| Figure | Table | n or k | Form | Crystal | Wavelength, (Micron) From | Wavelength, (Micron) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 5-103 | | n, k | Bulk | Single | 20 | 85 | | Wavelength |
| 5-104 | | n | Bulk | Polycryst | 0.8 | 2.5 | | Wavelength |
| 5-105 | | n | Bulk | Polycryst | 2.0 | 13 | 198°K | Wavelength |
| 5-106 | | n | Bulk | Polycryst | 2.0 | 14 | 295°K | Wavelength |
| 5-107 | 5-41 | n | Bulk | Polycryst | 1.0 | 29 | | Wavelength |
| 5-108 | | n, k | Bulk | Polycryst | 10 | 120 | 90°K | Wavelength |
| 5-109 | | n, k | Bulk | Polycryst | 10 | 125 | 300°K | Wavelength |
| 5-110 | | n, k | Bulk | Polycryst | 28 | 67 | 77, 290°K | Wavelength |
| 5-111 | | n, k | Bulk | Polycryst | 28 | 67 | 77, 290°K | Wavelength |
| | 5-42 | n | Film | * | 0.8 | 1.9 | | Wavelength |
| 5-112 | | n, k | Bulk | Single | 20 | 85 | | Temperature |
| 5-113 | | n | Bulk | Polycryst | 2.0 | 13 | 198°K | Temperature |
| 5-114 | | n | Bulk | Polycryst | 2.0 | 14 | 295°K | Temperature |
| 5-115 | | n, k | Bulk | Polycryst | 10 | 120 | 90°K | Temperature |
| 5-116 | | n, k | Bulk | Polycryst | 10 | 125 | 300°K | Temperature |
| 5-117 | | n, k | Bulk | Polycryst | 28 | 67 | 77, 290°K | Temperature |
| 5-118 | | n, k | Bulk | Polycryst | 28 | 67 | 77, 290°K | Temperature |

*Not stated

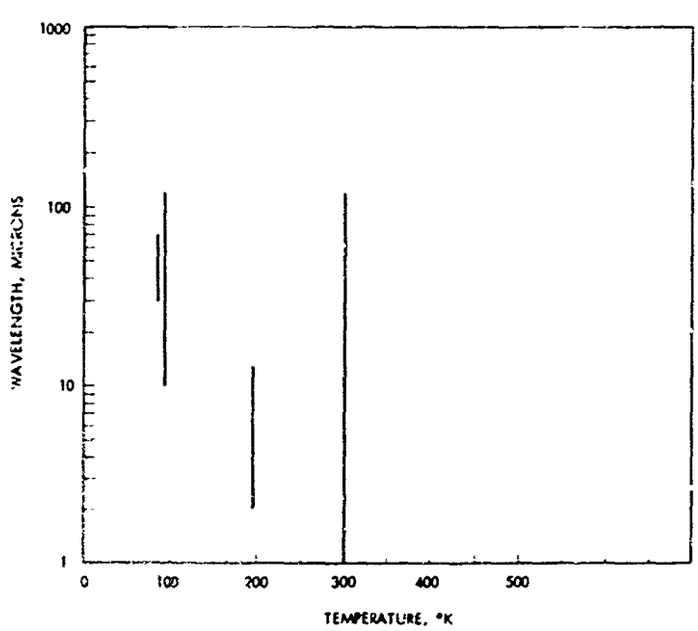
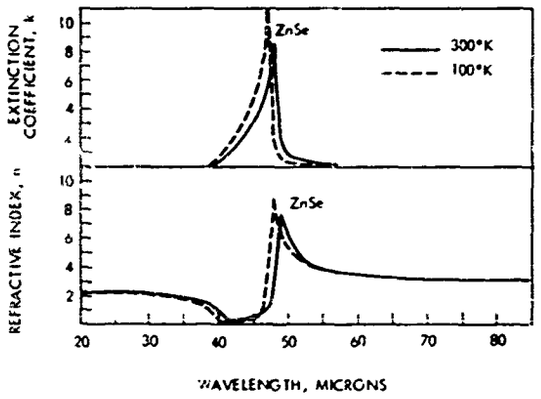



Figure 5-102. Wavelength and Temperature Range for Zinc Selenide Data

**PARAMETER:** Wavelength

**MATERIAL:** Zinc Selenide




**FORM** Bulk, Single Crystal

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 20 - 85 μ

**TEMPERATURE** 100, 300 °K

**METHOD** Reflection

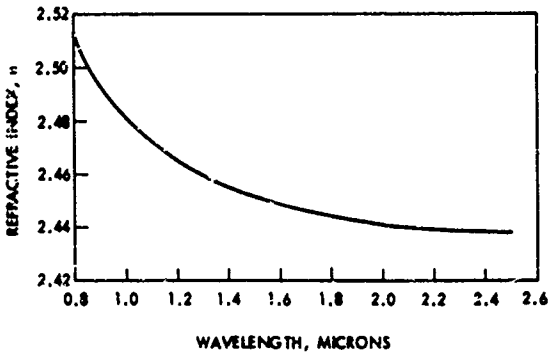
**REFERENCE** Manabe, et al. (28526)

**REMARKS**

Figure 5-103

PARAMETER: Wavelength

MATERIAL: Zinc Selenide




FORM Bulk, Polycrystalline

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 2.5 μ

TEMPERATURE ~298 °K

METHOD Deviation

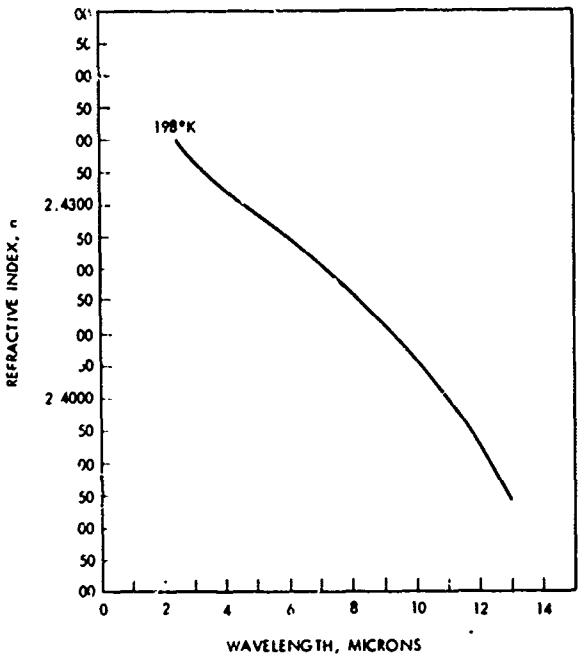
REFERENCE Marple (15085)

REMARKS Crystal was prepared by bonding two to four single crystals together.

Figure 5-104

PARAMETER: Wavelength

MATERIAL: Zinc Selenide




FORM Bulk, Polycrystalline

THICKNESS NA (Wedge) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 14 μ

TEMPERATURE 198, 295 °K

METHOD Deviation

REFERENCE Hilton and Jones [1967]

REMARKS

Figure 5-105

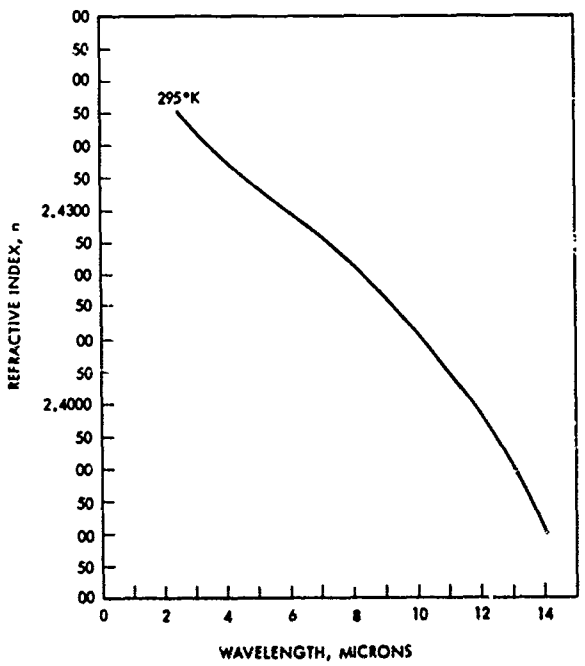
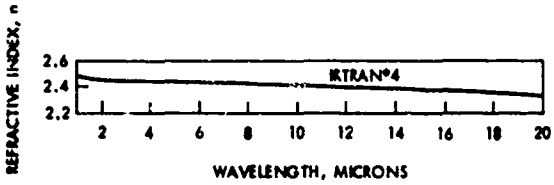



Figure 5-106

PARAMETER: Wavelength

MATERIAL: Zinc Selenide




FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 20 μ

TEMPERATURE 298 °K

METHOD Not stated

REFERENCE Kodak [1967]

REMARKS IRTRAN-4 material

Figure 5-107

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.0000 | 2.485 | 7.0000 | 2.423 |
| 1.2500 | 2.466 | 7.2500 | 2.422 |
| 1.5000 | 2.456 | 7.5000 | 2.421 |
| 1.7500 | 2.450 | 7.7500 | 2.419 |
| 2.0000 | 2.447 | 8.0000 | 2.418 |
| 2.2500 | 2.444 | 8.2500 | 2.417 |
| 2.5000 | 2.442 | 8.5000 | 2.416 |
| 2.7500 | 2.441 | 8.7500 | 2.415 |
| 3.0000 | 2.440 | 9.0000 | 2.413 |
| 3.2500 | 2.438 | 9.2500 | 2.411 |
| 3.5000 | 2.437 | 9.5000 | 2.410 |
| 3.7500 | 2.436 | 9.7500 | 2.409 |
| 4.0000 | 2.435 | 10.0000 | 2.407 |
| 4.2500 | 2.434 | 11.0000 | 2.401 |
| 4.5000 | 2.433 | 12.0000 | 2.394 |
| 4.7500 | 2.433 | 13.0000 | 2.386 |
| 5.0000 | 2.432 | 14.0000 | 2.378 |
| 5.2500 | 2.431 | 15.0000 | 2.370 |
| 5.5000 | 2.430 | 16.0000 | 2.361 |
| 5.7500 | 2.429 | 17.0000 | 2.352 |
| 6.0000 | 2.428 | 18.0000 | 2.343 |
| 6.2500 | 2.426 | 19.0000 | 2.333 |
| 6.5000 | 2.425 | 20.0000 | 2.323 |
| 6.7500 | 2.424 | | |

Table 5-41

PARAMETER: Wavelength

MATERIAL: Zinc Selenide

FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 10 - 125 μ

TEMPERATURE 90, 300 °K

METHOD Reflection

REFERENCE Hadni, et al. (29510)

REMARKS

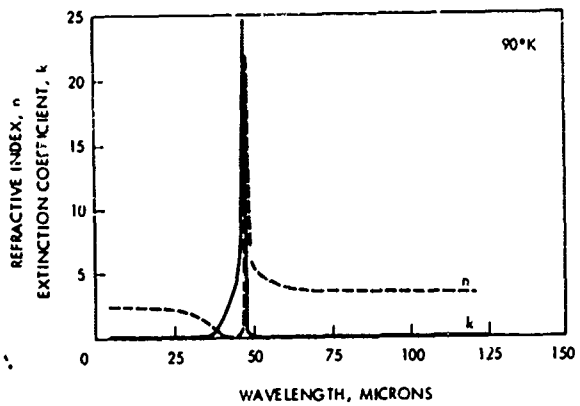



Figure 5-108

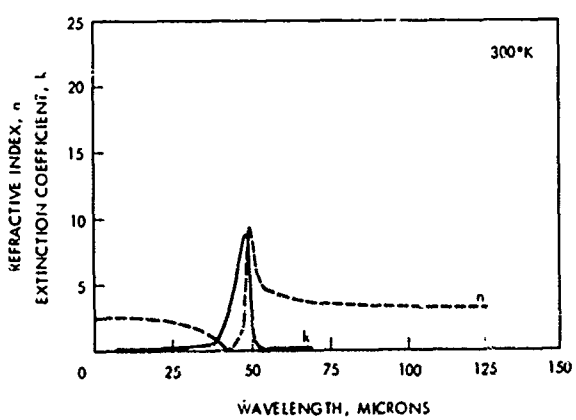



Figure 5-109

PARAMETER: Wavelength

MATERIAL: Zinc Selenide

FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

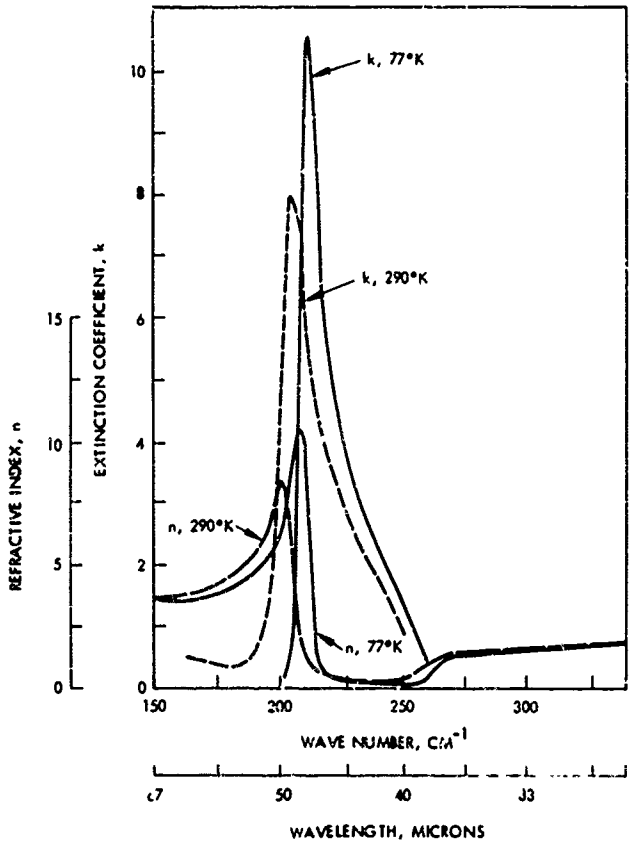
WAVELENGTH 28 - 67 μ

TEMPERATURE 77, 290 °K

METHOD Reflection

REFERENCE Hadni, et al. (34136)

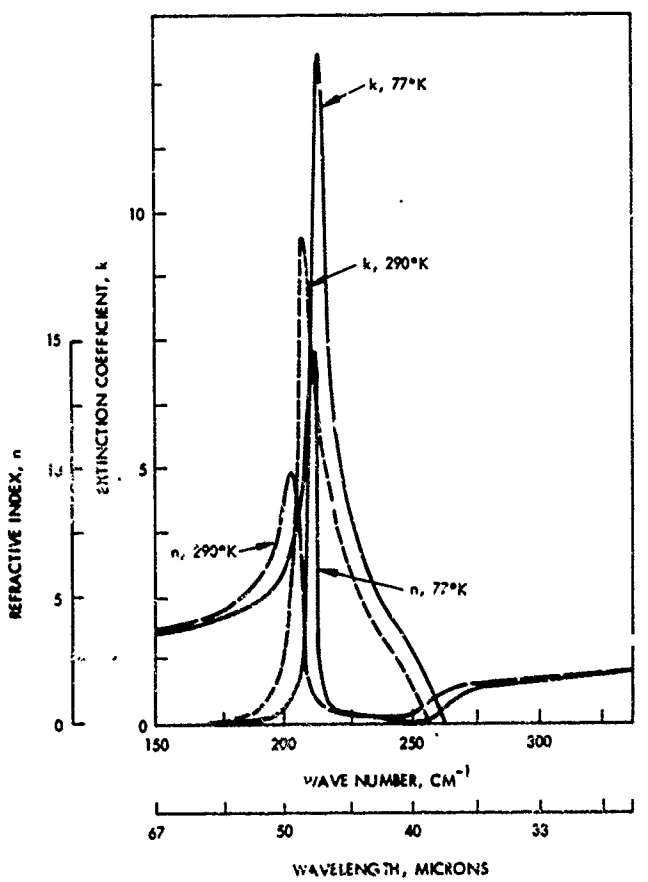
REMARKS




Calculated by Kramers-Kronig Method

Figure 5-110

Published with permission
Copyright © 1968 Akademie Verlag




Calculated by Lorentz Oscillator Theory

Figure 5-111

PARAMETER: Wavelength

MATERIAL: Zinc Selenide

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.8 | 2.50 |
| 0.9 | 2.47 |
| 1.0 | 2.46 |
| 1.1 | 2.45 |
| 1.2 | 2.44 |
| 1.3 | 2.43 |
| 1.5 | 2.42 |
| 1.7 | 2.41 |
| >1.9 | 2.40 |

FORM Film

THICKNESS ~ $0.8 \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.9 μ

TEMPERATURE ~298 °K

METHOD Interference

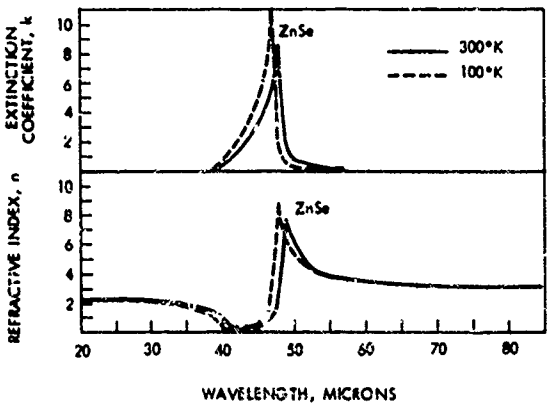
REFERENCE Fischer, et al. (15559)

REMARKS Evaporated film on borosilicate glass substrate.

Table 5-42

PARAMETER: Temperature

MATERIAL: Zinc Selenide




FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 20 - 85 μ

TEMPERATURE 100, 300 °K

METHOD Reflection

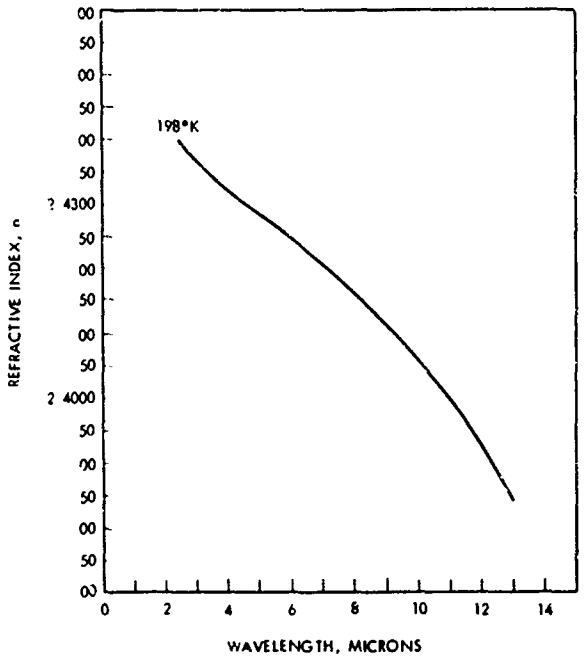
REFERENCE Manabe, et al. (28526)

REMARKS

Figure 5-112

PARAMETER: Temperature

MATERIAL: Zinc Selenide




FORM Bulk, Polycrystalline

THICKNESS NA (Wedge) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 14 μ

TEMPERATURE 198, 295 °K

METHOD Deviation

REFERENCE Hilton and Jones [1967]

REMARKS

Figure 5-113

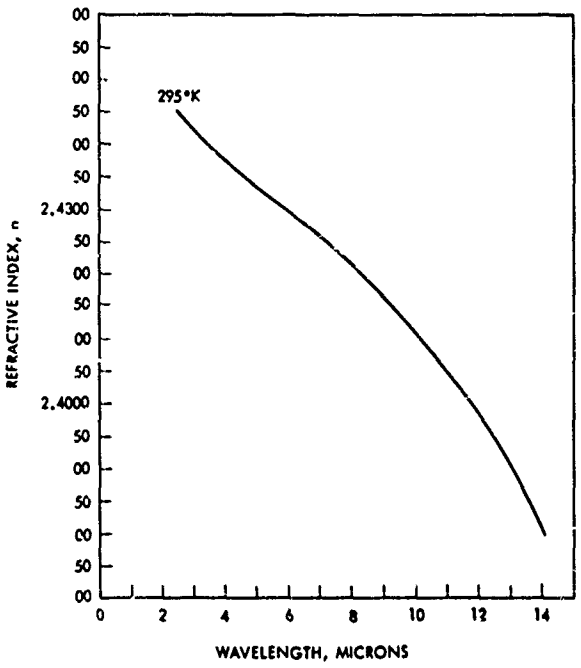
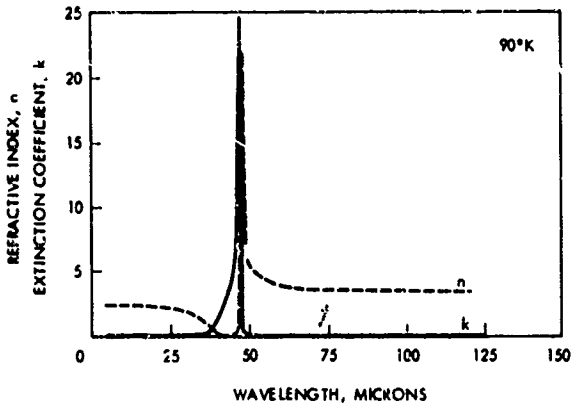



Figure 5-114

PARAMETER: Temperature

MATERIAL: Zinc Selenide




FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 10 - 125 μ

TEMPERATURE 90, 300 °K

METHOD Reflection

REFERENCE Hadni, et al. (29510)

REMARKS

Figure 5-115

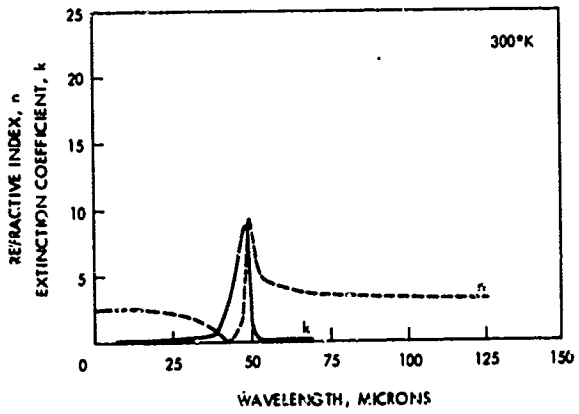
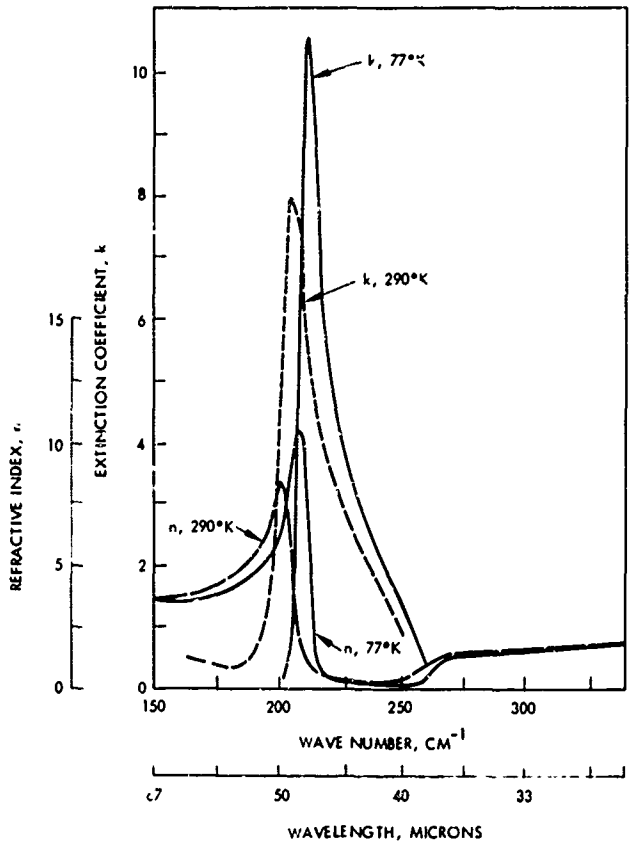



Figure 5-116

PARAMETER: Temperature

MATERIAL: Zinc Selenide

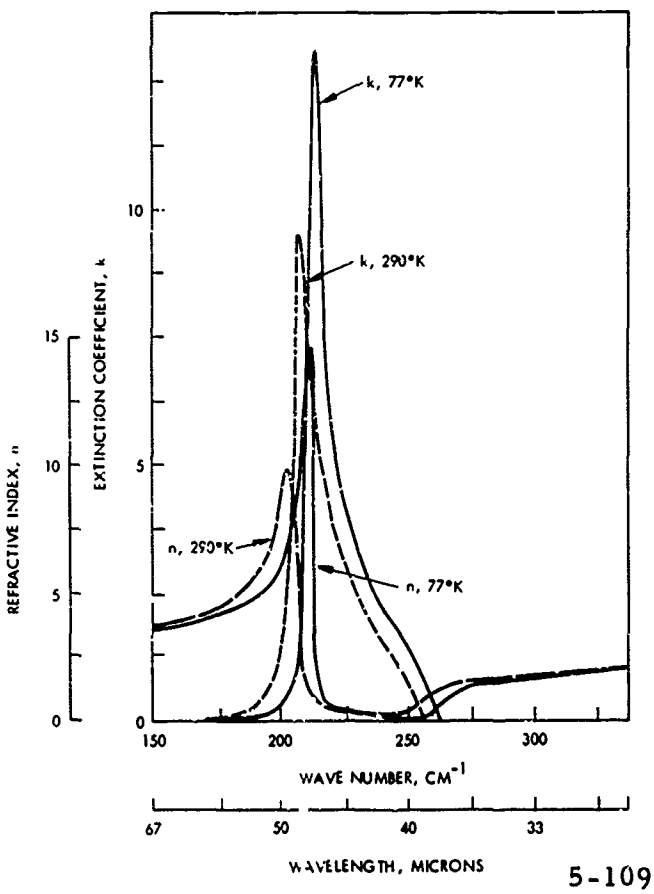



| | |
|---|---|
| FORM | Bulk, Polycrystalline |
| THICKNESS | Not stated mm |
| RAY | ORDINARY ☒, EXTRAORDINARY ☐ |
| WAVELENGTH | 28 - 67 μ |
| TEMPERATURE | 77, 290 °K |
| METHOD | Reflection |
| REFERENCE | Hadni, et al. (34136) |
| REMARKS | ITRAN-4 material |

Calculated by Kramers-Kronig method.

Figure 5-117

Published with permission
Copyright ©1960 Akademie Verlag




Calculated by Lorentz Oscillator Method

Figure 5-118

# CHAPTER 6

# REFRACTIVE INDEX DATA FOR SILICA-QUARTZ-SILICON DIOXIDE

## GENERAL

This Chapter describes a class of materials called "quartz", "silica", or "silicon dioxide".

There exists in quartz and silica a great deal of confusion in nomenclature. Laufer [1965] distinguishes five materials which in turn are described by many terms. Table 6-1 presents Laufer's terms for the five materials.

Modern optical glasses are made under adequate quality control and many recent publications do not distinguish materials in the manner shown in Table 6-1. Therefore this Report distinguishes only two types of quartz or silica:

1. Crystalline Silica
2. Fused Silica

Table 6-1. Terms Used for Five Silica Materials

| High Silica Glass | Natural Quartz | Cultured Quartz | Transparent Vitreous Silica | Translucent Fused Silica |
|---|---|---|---|---|
| Silica Glass | Quartz | Cultured Quartz | Quartz | Translucent Fused Quartz |
| Vitreous Silica | Crystalline Quartz | Synthetic Quartz | Quartz Glass | (Quarzgut, in German) |
| High Silica Glass | Quartz Crystal | Synthetic Quartz Crystal | (Quarzglas, in German) | Translucent Fused Silica |
| | Natural Quartz | | Fused Quartz | Fused Silica |
| | Rock Crystal | | Vitreous Quartz | Translucent Vitreous Silica |
| | | | Fused Quartz Glass | Vitreous Silica |
| | | | Optical Quartz Glass | |
| | | | Optical Fused Quartz | |
| | | | Clear Fused Quartz | |
| | | | Transparent Fused Quartz | |
| | | | Fused Silica | |
| | | | Synthetic Fused Silica | |
| | | | Transparent Fused Silica | |
| | | | Clear Fused Silica | |
| | | | Silica Glass | |
| | | | Transparent Vitreous Silica | |
| | | | Clear Vitreous Silica | |
| | | | Vitreous Silica | |

## SILICA, CRYSTALLINE

### INTRODUCTION

Crystalline silica, also called $\alpha$-quartz, is the only crystalline form of silica that is stable below 846°K at atmospheric pressure. It is a uniaxial birefringent crystal (hexagonal) that has a resistivity of approximately $10^{15}$ ohm-cm at 300°K. Crystalline silica exhibits strong optical absorption due to lattice absorption bands between 5 and 37 microns in wavelength, becoming transparent again from 50 to 1000 microns, as shown in Figure 1-4. The transmittance in the far infrared has led to the use of this material as window material in this region and for eliminating high-order radiation in far infrared grating spectrometers. Other applications of crystalline silica include piezoelectric crystals and electromechanical transducers.

Most high grade natural crystalline silica is obtained from Brasil. Material of similar quality has been synthesized by hydrothermal growing. The physical properties of crystalline silica are summarized in Table 1-1.

### DATA

The data for crystalline silica are listed in Table 6-2 and detailed in Figures 6-1 to 6-15 and Tables 6-3 to 6-6. Table 6-3 represents a composite of early data for the near infrared region. The wavelengths covered in the data are from 1 to 600 microns and all data were gathered at room temperature. In additional to the refractive index for the ordinary ray, a great deal of refractive index data for the extraordinary ray is included. In general, the data show good agreement in refractive indices.

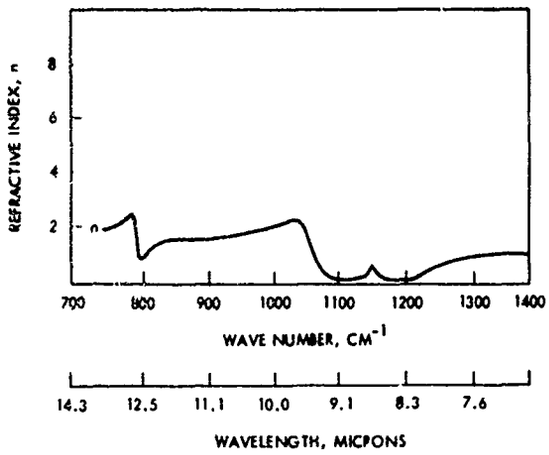
**PRECEDING PAGE BLANK**

Table 6-2. List of Crystalline Silica Data

| Figure | Table | $n_o$ | $n_e$ | Form | Crystal | Wavelength (Microns) From | Wavelength (Microns) To | Parameter |
|---|---|---|---|---|---|---|---|---|
| 6-1 | | X | | Bulk | | 7 | 14 | Wavelength |
| 6-2 | | X | | Bulk | | 5 | 14 | Wavelength |
| 6-3 | | X | | Bulk | | 6 | 33 | Wavelength |
| 6-4 | | | X | Bulk | | 6 | 33 | Wavelength |
| 6-5 | | X | X | Bulk | | 6 | 35 | Wavelength |
| | 6-3 | X | X | Bulk | | 1 | 4 | Wavelength |
| 6-6 | | X | | Bulk | | 80 | 300 | Wavelength |
| 6-7 | | | X | Bulk | | 80 | 300 | Wavelength |
| 6-8 | | X | | Bulk | | 27 | 63 | Wavelength |
| 6-9 | | | X | Bulk | | 27 | 63 | Wavelength |
| 6-10 | | X | | Bulk | | 50 | 500 | Wavelength |
| 6-11 | | | X | Bulk | | 50 | 500 | Wavelength |
| 6-12 | | X | | Bulk | | 40 | 500 | Wavelength |
| | 6-4 | X | | Bulk | | 70 | 300 | Wavelength |
| | 6-5 | X | X | Bulk | | 100 | 300 | Wavelength |
| 6-13 | | X | | Bulk | | 180 | 600 | Wavelength |
| 6-14 | | | X | Bulk | | 180 | 600 | Wavelength |
| 6-15 | | X | | Bulk | | 180 | 500 | Wavelength |
| | 6-6 | X | | Bulk | | 337 | 337 | Wavelength |

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline




FORM Bulk

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7-14 μ

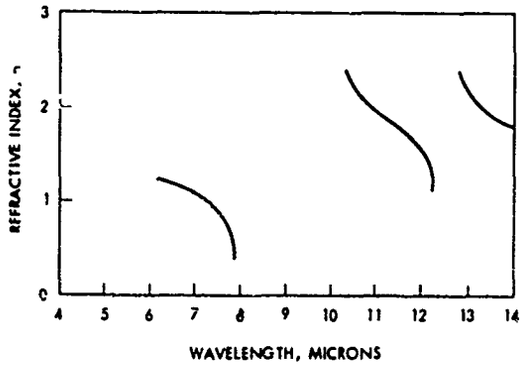
TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Simon (39827)

REMARKS Crystal cut perpendicular to the optical axis

Figure 6-1




Published with permission
Copyright © 1951 Commission des
Publications françaises de Physique

THICKNESS 0.025 - 0.05 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 5-14 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Ramadier-Delbès (39712)

REMARKS

Figure 6-2

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline

FORM Bulk

THICKNESS 0.030 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 6-33 μ

TEMPERATURE 298 °K

METHOD Reflection

REFERENCE Haefele (40240)

REMARKS

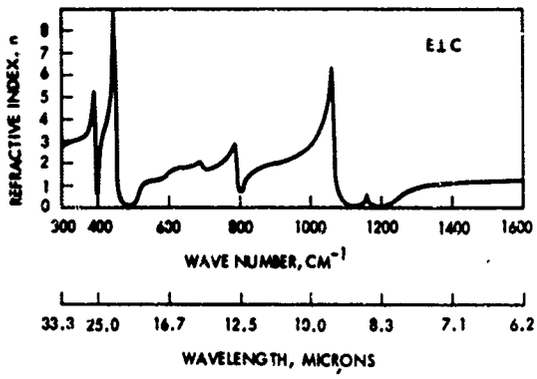



Figure 6-3

Published with permission
Copyright © 1962 Springer-Verlag

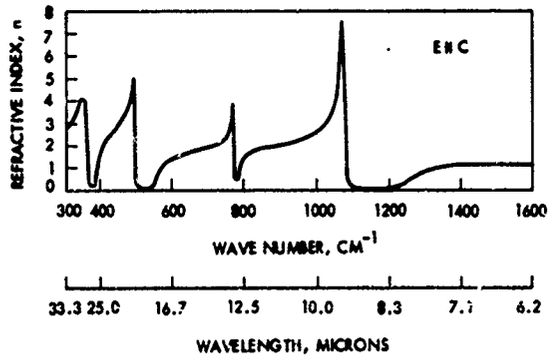
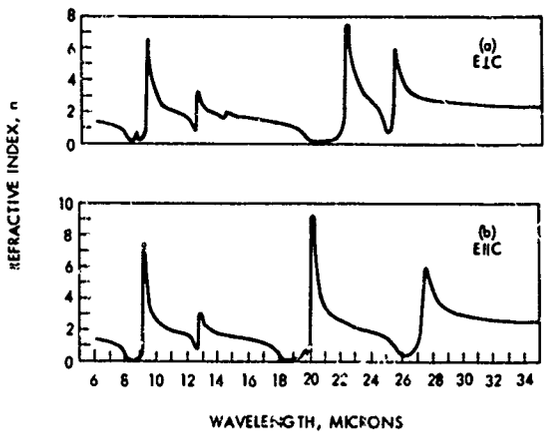



Figure 6-4

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline




THE REFRACTIVE INDEX OF QUARTZ FOR THE ORDINARY RAY (a) AND THE EXTRAORDINARY RAY (b) AS OBTAINED FROM THE DISPERSION ANALYSIS OF THE REFLECTIVITY.

FORM Bulk

THICKNESS 0.0262 mm

RAY ORDINARY ☒, EXTRAORDINARY ☒

WAVELENGTH 6-35 μ

TEMPERATURE 297 °K

METHOD Reflectivity

REFERENCE Spitzer & Kleinman (1869b)

REMARKS α-quartz

Figure 6-5

| Wavelength, (Microns) | Refractive Index $n_o$ | Refractive Index $n_o$ | Ref |
|---|---|---|---|
| 1.0417 | 1.53442 | 1.54317 | a |
| 1.0973 | 1.53366 | 1.54238 | a |
| 1.1592 | 1.53283 | 1.54152 | a |
| 1.2288 | 1.53192 | 1.54057 | a |
| 1.3070 | 1.53090 | 1.53951 | a |
| 1.3685 | 1.53011 | 1.53860 | a |
| 1.3958 | 1.52977 | 1.53632 | a |
| 1.4792 | 1.52865 | 1.53716 | a |
| 1.5414 | 1.52781 | 1.53630 | a |
| 1.6146 | 1.52679 | 1.53524 | a |
| 1.6815 | 1.52583 | 1.53422 | a |
| 1.7437 | 1.5248 | 1.53319 | a |
| 1.9457 | 1.52184 | 1.53004 | a |
| 2.0531 | 1.52005 | 1.52823 | a |
| 2.60 | 1.50966 | – | b |
| 3.00 | 1.49953 | – | b |
| 3.50 | 1.48451 | – | b |
| 4.00 | 1.46617 | – | b |
| 4.20 | 1.4569 | – | c |

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☒

WAVELENGTH 1.0 – 4.2 μ

TEMPERATURE 291 °K

METHOD Not stated

REFERENCE Smakula [1952]

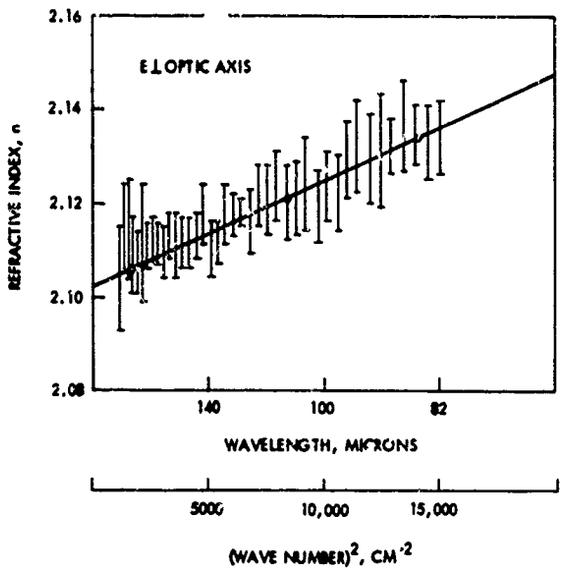
REMARKS References for this Table:

(a) Carvallo, A., Compt. rend. Vol. 126, (1898), p. 728.
(b) Kohlrausch, F., "Praktische Physik," Vol. II, 18th Ed., B. G. Teubner, Leipzig, (1943), p. 528.
(c) Rubens, H., Wied. Ann., Vol. 54, (1895), p. 488.

Table 6-3

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline




FORM Bulk

THICKNESS ~1 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 80 – 300 μ

TEMPERATURE 298 °K

METHOD Transmission

REFERENCE Roberts & Coon (18253)

REMARKS Brazilian Quartz

Figure 6-6

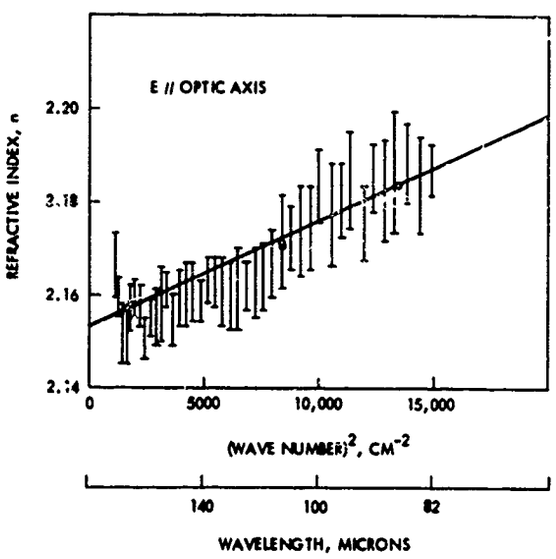



Figure 6-7

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline

FORM Bulk

THICKNESS 0.0766 mm

RAY ORDINARY ☒, EXTRAORDINARY ☒

WAVELENGTH 27 – 63 μ

TEMPERATURE 301 °K

METHOD Interference

REFERENCE Russell & Bell (28888)

REMARKS

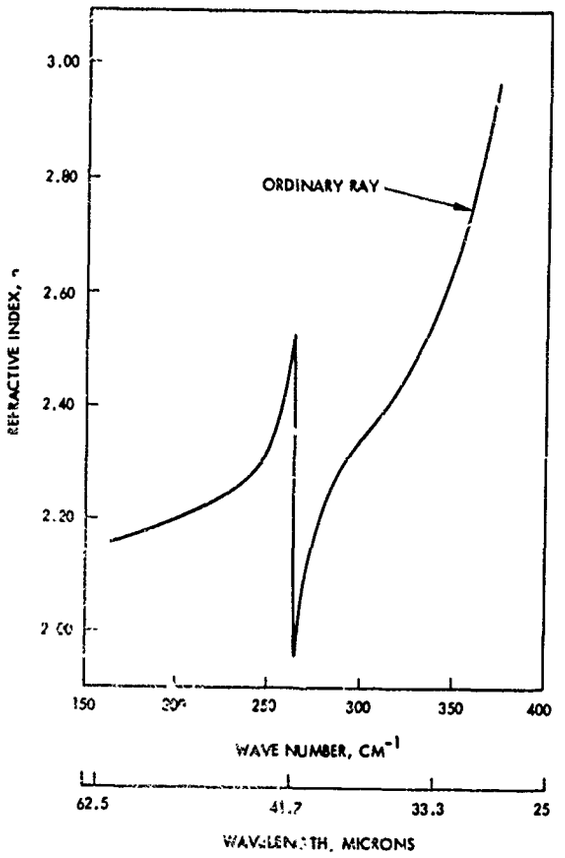



Figure 6-8

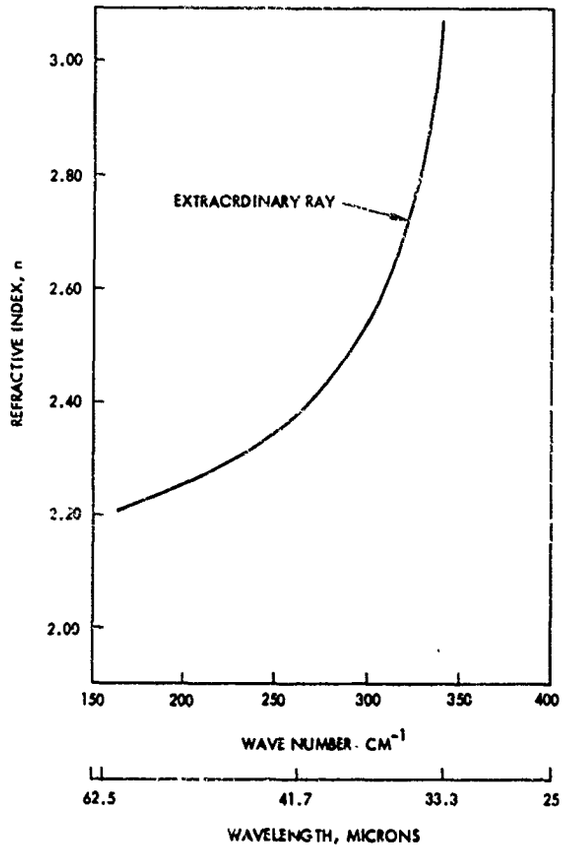



Figure 6-9

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline

FORM Bulk

THICKNESS 0.255 mm

RAY ORDINARY ☒ EXTRAORDINARY ☒

WAVELENGTH 100 – 300 μ

TEMPERATURE 300 °K

METHOD Interference

REFERENCE Berman & Zhukov (36032)

REMARKS

(a) crystal cut ⊥ to optical axis

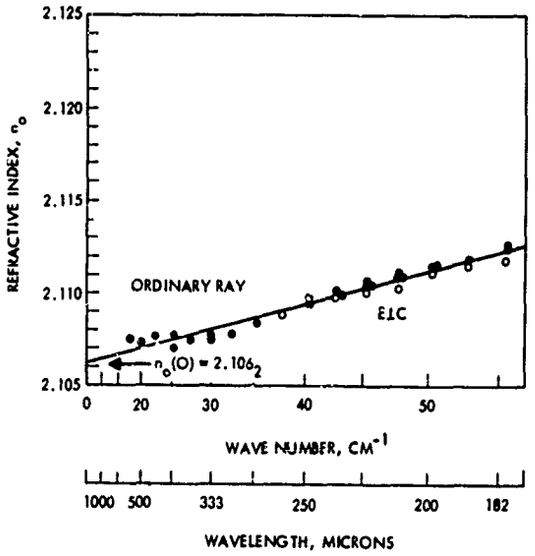
(b) crystal cut ∥ to optical axis, (X cut)

| Wavelength, Microns | Refractive Index, Ordinary Ray ($n_o$) | Refractive Index, Extraordinary Ray ($n_e$) |
|---|---|---|
| 100-300 | 2.10 ± 0.03[a] | – |
| 165-240 | 2.11 ± 0.03[b] | 2.16 ± 0.02[b] |

Table 6-5

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline




Determination of the extrapolated, zero-frequency ordinary- and extraordinary-ray refractive indices of quartz. The extrapolated values, $n_o(0) = 2.1062$ and $n_e(0) = 2.1538$, have an experimental uncertainty of ±0.001, which is much larger than is apparent from the consistency of the data

FORM Bulk

THICKNESS 1.0497, 4.7873 mm

RAY ORDINARY ☐, EXTRAORDINARY ☒

WAVELENGTH 180 – 600 μ

TEMPERATURE 301 °K

METHOD Interference

REFERENCE Russell & Bell (28888)

REMARKS

Figure 6-13

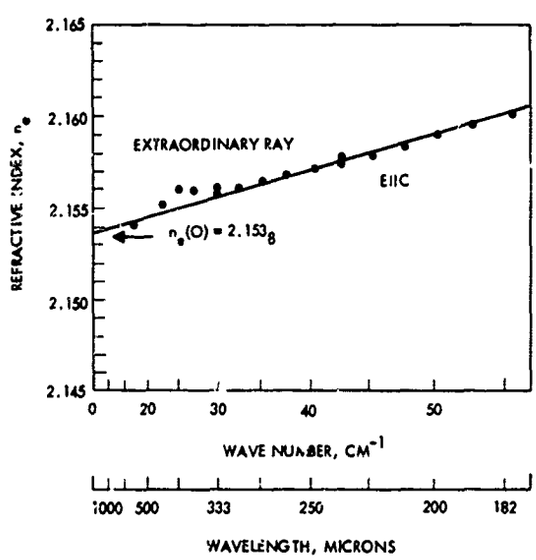
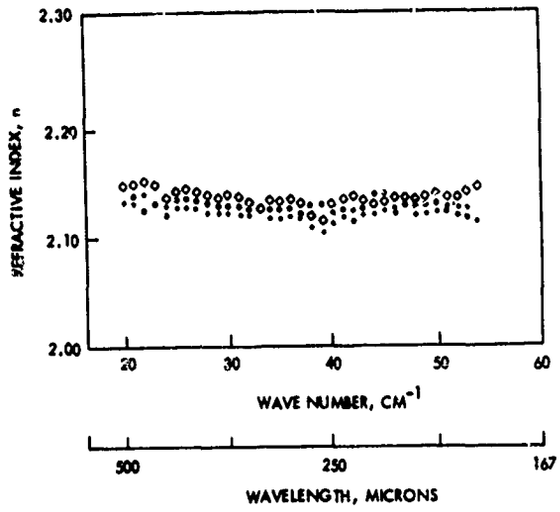



Figure 6-14

PARAMETER: Wavelength

MATERIAL: Silica Crystalline




Published with permission
Copyright © 1963 MacMillan (Journals) Ltd.

FORM Bulk

THICKNESS 0.48 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 180 – 500 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Chamberlain (40179)

REMARKS ◇run 1; O run 2; ● run 3

Figure 6-15

| Wavelength, Microns | Refractive Index, n |
|---|---|
| 337 | 2.132 ± 0.026 |

THICKNESS 3-7 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 337 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Chamberlain & Gebbie(40177)

REMARKS Use of CN maser as radiation source.

Table 6-6

PARAMETER: Wavelength

MATERIAL: Silica, Crystalline

FORM Bulk

THICKNESS 1.0497, 4.7873 mm

RAY ORDINARY ☒, EXTRAORDINARY ☒

WAVELENGTH 50 – 500 μ

TEMPERATURE 301 °K

METHOD Interference

REFERENCE Russell & Bell (28888)

REMARKS

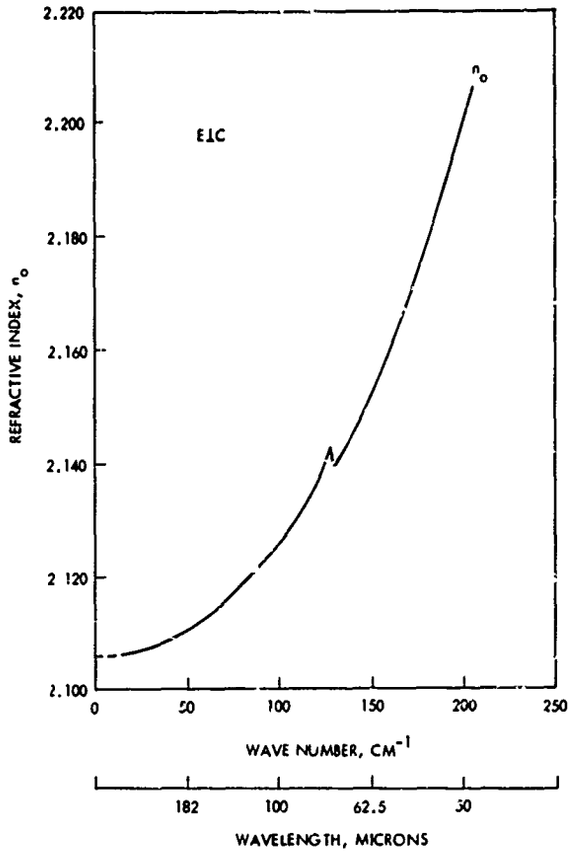



Figure 6-10

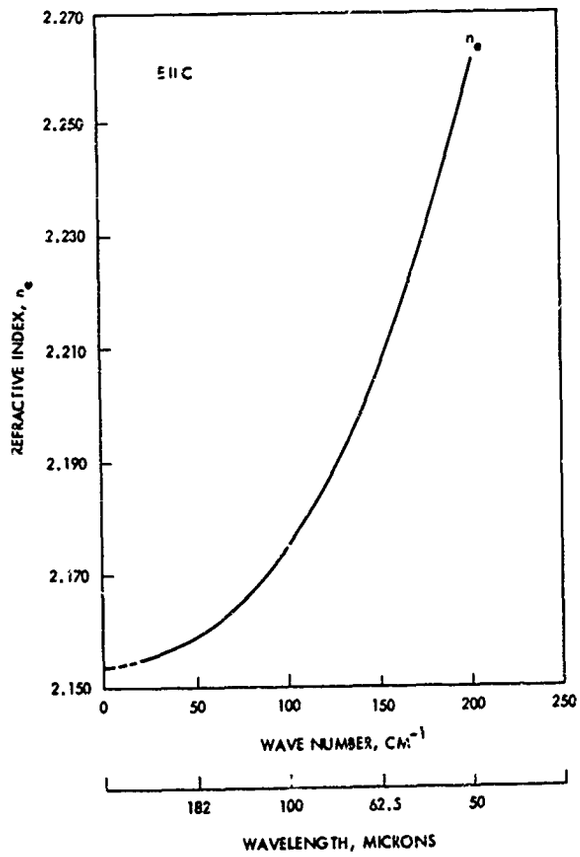
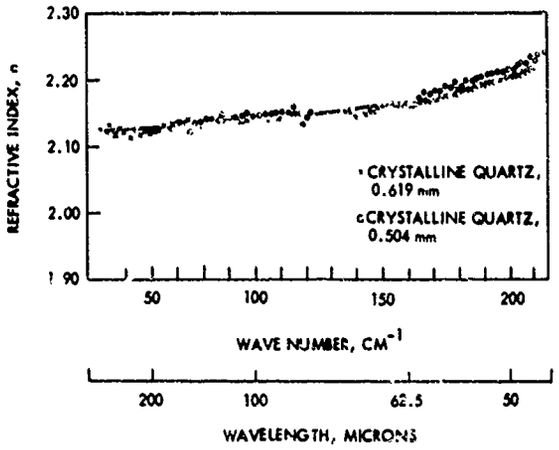



Figure 6-11

PARAMETER: Wavelength

MATERIAL: Silica Crystalline




Published with permission
Copyright © 1961 Springer-Verlag

FORM Bulk

THICKNESS ~0.6 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 40 – 500 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Geick (39706)

REMARKS

Figure 6-12

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 70-300 | 2.2 ± 0.02 |

THICKNESS 1, 2 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 70 – 300 μ

TEMPERATURE 298 °K

METHOD Interference

REFERENCE Poinsot, et al., (40710)

REMARKS

Table 6-4

## SILICA, FUSED

### INTRODUCTION

Fused silica is considered to be a glass and in common with other glasses, its transmission spectrum shows a deep absorption near 2.8 microns and poor transmission at longer wavelengths (Figure 1-5). The absorption in this region is caused by O-H stretching bands. Fused silica is used in innumerable technical applications because of its optical, thermal, mechanical and electrical properties.

Classically, fused silica is prepared by fusion of crystalline silica. Material of very high pruity can be made by hydrolysis of silicon tetrachloride at high temperature where the product, (fused silica) is deposited on a substrate.

The physical properties of fused silica are summarized in Table 1-1 and its transmission in the far infrared is plotted in Figure 1-6.

### DATA

The data for fused silica are listed in Table 6-7 and their temperature range is plotted in Figure 6-16. Refractive index spectra for bulk fused silica are offered in Figures 6-17 to 6-23 and Tables 6-8 to 6-15; similar data for film fused silica are provided in Figures 6-24 and 6-25. Comparison of the data shows good agreement to approximately eight microns with a wider spread in data at longer wavelengths. The meager film data show good agreement with bulk data. The temperature dependence of the refractive index of bulk fused silica is the subject of Table 6-16 and Figure 6-26, while film data are shown in Figure 6-27. Figure 6-27 indicates an increase in refractive index with temperature at wavelengths below nine microns, and the opposite effect at longer wavelengths. The effects of ultraviolet radiation or simulated Apollo mission space environment are the subjects of Figure 6-28 and Table 6-17, respectively.

Table 6-7. List of Fused Silica Data

| Figure | Table | n, k | Form | Crystal | Wavelength (microns) From | To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 6-17 | | n | Bulk | | 0.4 | 3.5 | | Wavelength |
| 6-18 | | n | Bulk | | 0.2 | 3.5 | | Wavelength |
| | 6-8 | n | Bulk | | 0.7 | 3.7 | | Wavelength |
| | 6-9 | n | Bulk | | 0.4 | 1.08 | | Wavelength |
| | 6-10 | n | Bulk | | 0.7 | 3.7 | | Wavelength |
| | 6-11 | n | Bulk | | 1.0 | 1.5 | | Wavelength |
| | 6-12 | n | Bulk | | 1.0 | 3.4 | | Wavelength |
| | 6-13 | n | Bulk | | 1.0 | 2.6 | | Wavelength |
| 6-19 | | n | Bulk | | 7.7 | 12 | | Wavelength |
| 6-20 | | n | Not Stated | | 6 | 100 | | Wavelength |
| 6-21 | | n | Not Stated | | 30 | 2000 | | Wavelength |
| | 6-14 | n | Bulk | | 50 | 400 | | Wavelength |
| 6-22 | | n | Bulk | | 85 | 200 | | Wavelength |
| 6-23 | | n | Bulk | | 111 | 600 | | Wavelength |
| | 6-15 | n, k | Bulk | | 2000 | 2000 | | Wavelength |
| 6-24 | | n | Film | | 0.2 | 1.6 | | Wavelength |
| 6-25 | | n | Film | | 7 | 11 | 291-1543°K | Wavelength |
| | 6-16 | n | Bulk | | 1.0 | 3.4 | 299-1101°K | Temperature |
| 6-26 | | dn/dT | Bulk | | 0.2 | 4.0 | 293-303 | Temperature |
| 6-27 | | n | Film | | 7 | 11 | 291-1543 | Temperature |
| 6-28 | | n | Film | | 0.2 | 1.5 | UV Light | Radiation |
| | 6-17 | n | Bulk | | 0.23 | 3.4 | Space Radiation | Radiation |

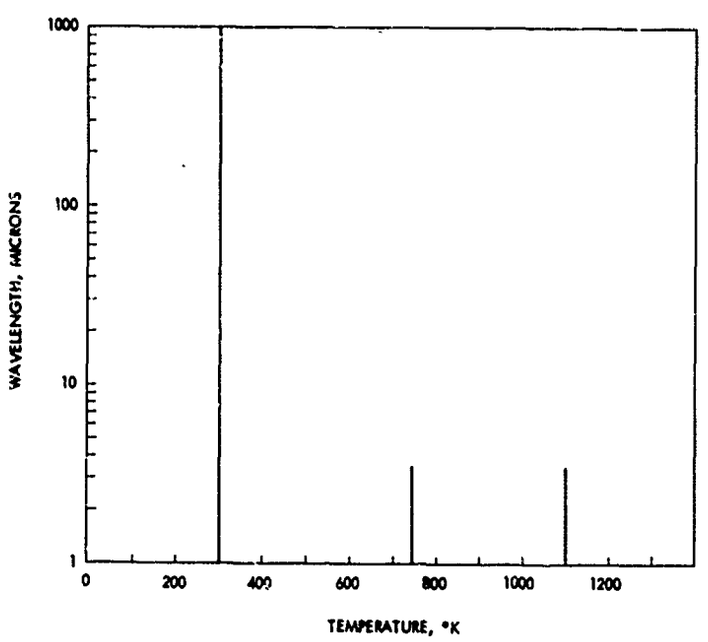
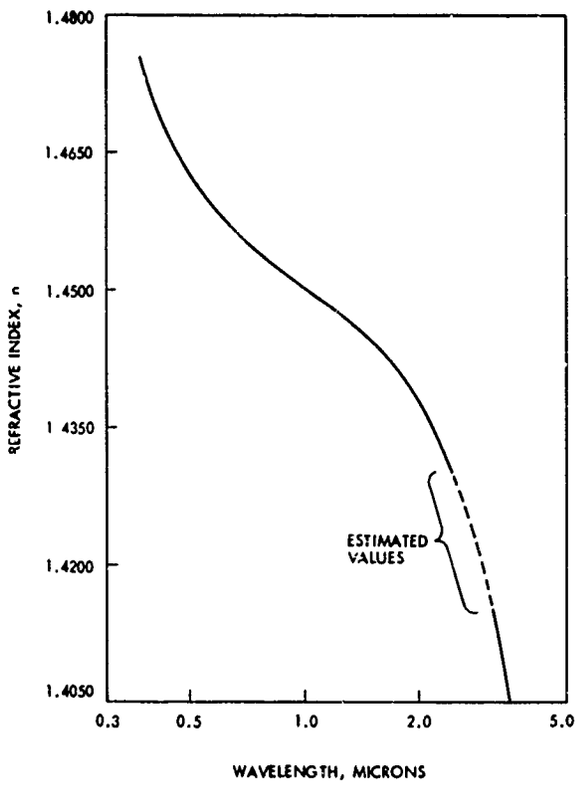



Figure 6-16. Wavelength and Temperature Range of Fused Silica Data

PARAMETER: Wavelength

MATERIAL: Silica, Fused




FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.4 - 3.5 μ

TEMPERATURE 297 °K

METHOD Deviation

REFERENCE Rodney and Spindler (39714)

REMARKS Heraeus B quartz

Most probable values of refractive indices of pure fused-quartz at 297°K for various wavelengths, computed from equation (1)

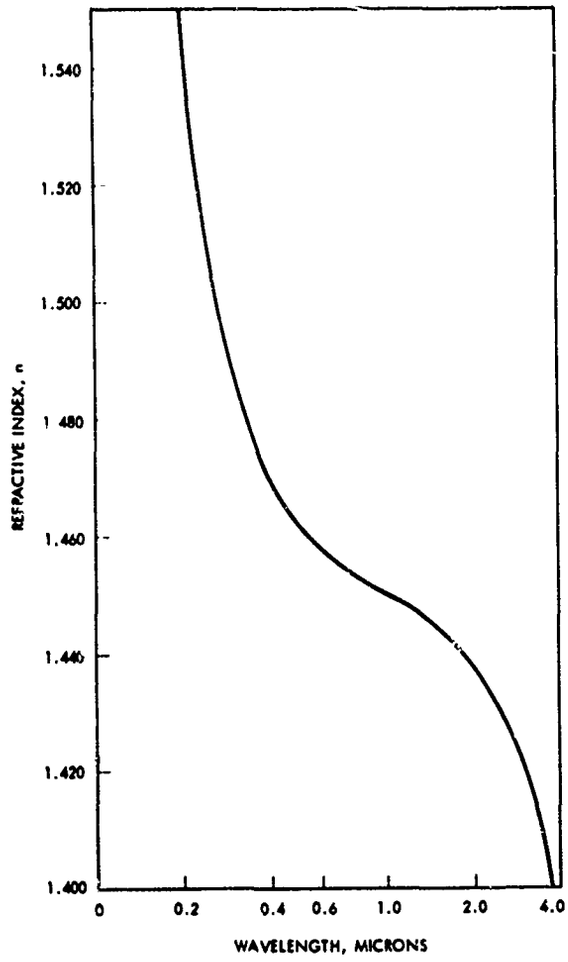
Figure 6-17

Equation (1) $$n^2 = 2.979864 + \frac{0.008777808}{\lambda^2 - 0.010609} - \frac{84.06224}{96.00000 - \lambda^2}$$

where $\lambda$ = wavelength in microns.

PARAMETER: Wavelength

MATERIAL: Silica, Fused




FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.2 - 3.5 μ

TEMPERATURE 293 °K

METHOD Deviation

REFERENCE Malitson (21758)

REMARKS The dispersion equation (2) is valid for interpolation to five decimal places over the measured wavelength range.

Figure 6-18

Equation (2)

$$n^2 - 1 = \frac{0.6961663\lambda^2}{\lambda^2 - (0.0684043)^2} + \frac{0.4079426\lambda^2}{\lambda^2 - (0.1162414)^2} + \frac{0.8974794\lambda^2}{\lambda^2 - (9.896161)^2},$$

where $\lambda$ = wavelength in microns.

PARAMETER: Wavelength

MATERIAL: Silica, Fused

FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 0.7 - 3.7 μ

TEMPERATURE 293 °K

METHOD Deviation

REFERENCE Malitson (21758)

REMARKS Computed refractive index for three products

Table 6-8. Computed Refractive Index and Residuals

| Wavelength microns | Spectral source | Computed index | C-D-G-E[a] residual X $10^6$ | Corning No. 7940 residual X $10^6$ | Dynasil residual X $10^6$ | General Electric No. 151 residual X $10^6$ |
|---|---|---|---|---|---|---|
| 0.706519 | He | 1.455145 | + 5 | + 10 | + 12 | + 7 |
| 0.852111 | Cs | 1.452465 | + 5 | + 8 | + 3 | + 5 |
| 0.894350 | Cs | 1.451835 | + 5 | + 11 | + 5 | + 10 |
| 1.01398 | Hg | 1.450242 | + 8 | + 6 | + 3 | + 6 |
| 1.08297 | He | 1.449405 | - 5 | + 8 | + 1 | + 9 |
| 1.12866 | Hg | 1.448869 | + 1 | + 7 | + 8 | + 9 |
| 1.3622 | Hg | 1.446212 | - 12 | - 6 | - 14 | - 12 |
| 1.39506 | Hg | 1.445836 | + 4 | - 1 | + 4 | - 3 |
| 1.4695 | Cs | 1.444975 | - 5 | + 3 | + 9 | + 10 |
| 1.52952 | Hg | 1.444268 | + 2 | + 8 | + 6 | 0 |
| 1.6606 | TCB[b] | 1.442670 | - 20 | - 14 | - 19 | - 11 |
| 1.681 | Poly[c] | 1.442414 | + 6 | - 2 | - 10 | + 8 |
| 1.6932 | Hg | 1.442260 | 0 | + 7 | - 6 | + 1 |
| 1.7091[illegible] | Hg | 1.442057 | + 3 | 0 | + 3 | - 1 |
| 1.81307 | Hg | 1.440699 | + 21 | - 7 | - 7 | + 6 |
| 1.97009 | Hg | 1.438[illegible] | + 1 | + 6 | + 12 | + 12 |
| 2.0581 | He | 1.437224 | 4 | - 3 | - 9 | - 11 |
| 2.1526 | TCB | 1.435769 | - 29 | - 22 | - 25 | - 24 |
| 2.32542 | Hg | 1.432928 | - 18 | - [illegible] | - 3 | - 6 |
| 2.4374 | TCB | 1.430954 | - 24 | - 23 | - 21 | - 14 |
| 3.2439 | Poly | 1.413118 | + 32 | + 21 | + 29 | + 25 |
| 3.2668 | Poly | 1.412505 | + 25 | + 20 | + 30 | + 25 |
| 3.3026 | Poly | 1.411535 | + 25 | + 32 | + 30 | + 28 |
| 3.422 | Poly | 1.408180 | + 20 | + 40 | + 42 | + 37 |
| 3.5070 | Poly | 1.405676 | - 16 | - 26 | - 20 | - 10 |
| 3.5564 | TCB | 1.404174 | - 24 | - 27 | - 29 | - 18 |
| 3.7067 | TCB | 1.399389 | - 19 | - 22 | - 14 | - 9 |
| Average of absolute values of residuals | | | 10.5 | 11.9 | 12.2 | 11.7 |

a Residuals for arithmetical-mean table of values compiled from experimental data of Corning (C), Dynasil (D), and General Electric (G. E.).
b TCB = 1, 2, 4 - Trichlorobenzene.
c Poly = Polystyrene.

PARAMETER: Wavelength (Cont'd from preceding page) MATERIAL: Silica, Fused

Table 6-9

Intracompany Comparison of Refractive Index Variation

| Wavelength, (Microns) | Product | | | | | | | | | | | |
|---|---|---|---|---|---|---|---|---|---|---|---|---|
| | Corning No. 7940 residual X $10^6$ | | | | Dynasil residual X $10^6$ | | | | General Electric No. 151 residual X $10^6$ | | | |
| | 1 | 2 | 3 | 4 | 1 | 2 | 3 | 4 | 1 | 2 | 3 | 4 |
| 0.4047 | 11 | 26 | 24 | 20 | 4 | 27 | 21 | 21 | 11 | 12 | -12 | 14 |
| 0.4861 | 16 | 27 | 16 | 21 | 5 | 29 | 19 | 21 | 7 | 15 | - 7 | 12 |
| 0.5461 | 14 | 24 | 22 | 17 | 5 | 35 | 25 | 16 | 11 | 12 | -13 | 12 |
| 0.5893 | 12 | 27 | 23 | 27 | 0 | 18 | 20 | 22 | 12 | 13 | - 8 | 12 |
| 0.6563 | 12 | 23 | 19 | 19 | 1 | 27 | 22 | 23 | 13 | 10 | - 7 | 14 |
| 0.7065 | 17 | 28 | 20 | 18 | 2 | 31 | 23 | 23 | 13 | 15 | -11 | 17 |
| 0.8944 | 11 | 26 | 22 | 19 | 3 | 31 | 19 | 25 | 11 | 12 | - 8 | 13 |
| 1.014 | 16 | 21 | 20 | 20 | 6 | 30 | 26 | 22 | 14 | 13 | -11 | 14 |
| 1.083 | 15 | 24 | 25 | 25 | 7 | 35 | 25 | 25 | 13 | 16 | - 9 | 12 |
| Av. Δn | 13.5 | 24.9 | 20.0 | 21.6 | 3.5 | 27.4 | 20.4 | 20.5 | 11.3 | 12.9 | - 9.6 | 13.2 |

NOTE: Numbered columns under each brand indicate individual specimens. The residuals are differences in the sixth decimal place of index between measured values and those computed by dispersion Equation (2). Each n is an average for the 18 wavelengths which were used. (See Figure 6-18 for Equation (2).

**PARAMETER:** Wavelength

**MATERIAL:** Silica, Fused

**FORM** Bulk

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.7 - 3.7 μ

**TEMPERATURE** 293 °K

**METHOD** Deviation

**REFERENCE** Brixner (29206)

**REMARKS** Computations based on data from Malitson (21758), giving average deviation of $4.3 \times 10^{-6}$.

| Wavelength, (Microns) | Spectral Source | Refractive Index: Four-term Fit to 180 Data Points: Computed | Corning | Dynasil | G.E. |
|---|---|---|---|---|---|
| 0.706519 | He | 1.455154 | + 1 | + 3 | - 2 |
| 0.852111 | Cs | 1.452475 | - 2 | - 7 | - 5 |
| 0.894350 | Cs | 1.451845 | + 2 | - 4 | + 1 |
| 1.01398 | Hg | 1.450250 | - 2 | - 5 | - 2 |
| 1.08297 | He | 1.449412 | + 1 | - 6 | + 7 |
| 1.12866 | Hg | 1.448875 | + 1 | + 2 | + 3 |
| 1.3622 | Hg | 1.446213 | - 7 | - 15 | - 13 |
| 1.39506 | Hg | 1.445837 | - 2 | + 3 | - 4 |
| 1.4695 | Cs | 1.444974 | + 4 | + 10 | + 11 |
| 1.52952 | Hg | 1.444266 | + 10 | + 8 | + 2 |
| 1.6606 | TCB[a] | 1.442666 | - 10 | - 15 | - 7 |
| 1.681 | Poly[b] | 1.442409 | + 3 | - 5 | + 13 |
| 1.6932 | Hg | 1.442255 | + 12 | - 1 | + 6 |
| 1.70913 | Hg | 1.442052 | + 5 | + 8 | + 4 |
| 1.81307 | Hg | 1.440692 | - 0 | - 0 | + 13 |
| 1.97009 | Hg | 1.438512 | + 14 | + 20 | + 20 |
| 2.0581 | He | 1.437216 | + 5 | - 1 | - 3 |
| 2.1526 | TCB | 1.435762 | - 15 | - 18 | - 17 |
| 2.32542 | Hg | 1.432922 | - 4 | + 3 | - 0 |
| 2.4374 | TCB | 1.430951 | - 20 | - 18 | - 11 |
| 3.2439 | Poly | 1.413138 | + 1 | + 9 | + 5 |
| 3.2668 | Poly | 1.412525 | - 0 | + 10 | + 5 |
| 3.3026 | Poly | 1.411554 | + 13 | + 11 | + 9 |
| 3.422 | Poly | 1.408194 | + 26 | + 28 | + 23 |
| 3.5070 | Poly | 1.405683 | - 33 | - 27 | - 37 |
| 3.5564 | TCB | 1.404175 | - 28 | - 30 | - 19 |
| 3.7067 | TCB | 1.399360 | + 7 | + 15 | + 20 |

a TCB = 1, 2, 4 - Trichlorobenzene.
b Poly = Polystyrene.

Table 6-10

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.0 - 1.5 μ

**TEMPERATURE** 298 °K

**METHOD** Deviation

**REFERENCE** Zernike (39697)

**REMARKS** Measurement on GE-101 silica, performed in air.

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 1.01398 | 1.45044 |
| 1.12866 | 1.44906 |
| 1.36728 | 1.44650 |
| 1.39506 | 1.44607 |
| 1.52952 | 1.44450 |

Table 6-11

PARAMETER: Wavelength

MATERIAL: Silica, Fused

Refractive Index

| Wavelength (Microns) | Refractive Index, n | | |
|---|---|---|---|
| | 299°K | 744°K | 1101°K |
| 1.01398 | 1.45039 | 1.45562 | 1.45960 |
| 1.12866 | 1.44903 | 1.45426 | 1.45820 |
| 1.254* | 1.44772 | 1.45283 | 1.45700 |
| 1.36728 | 1.44635 | 1.45140 | 1.45549 |
| 1.470* | 1.44524 | 1.45031 | 1.45440 |
| 1.52452 | 1.44444 | 1.44961 | 1.45352 |
| 1.660* | 1.44307 | 1.44799 | 1.45174 |
| 1.701 | 1.44230 | 1.44733 | 1.45140 |
| 1.981* | 1.43863 | 1.44361 | 1.44734 |
| 2.262* | 1.43430 | 1.43933 | 1.44306 |
| 2.553* | 1.42949 | 1.43450 | 1.43854 |
| 3.00* | 1.41995 | 1.42495 | 1.42877 |
| 3.245* | 1.41353 | 1.41893 | 1.42243 |
| 3.37* | 1.40990 | 1.41501 | 1.41915 |

$\delta n = 23 \times 10^{-5}$ (experimental error)

*Wavelength determination by narrow band interference filter.

FORM Bulk

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 3.4 μ

TEMPERATURE 299 - 1101 °K

METHOD Deviation

REFERENCE Neu, et al. (40260)

REMARKS Corning Code 7940 silica

Table 6-12

| Wavelength, (Microns) | Refractive Index, n | Reference |
|---|---|---|
| 1.028 | 1.450 | a |
| 1.196 | 1.448 | b |
| 1.370 | 1.446 | b |
| 1.560 | 1.444 | b |
| 1.722 | 1.442 | c |
| 1.870 | 1.440 | b |
| 2.010 | 1.438 | b |
| 2.145 | 1.436 | b |
| 2.270 | 1.434 | b |
| 2.390 | 1.432 | b |
| 2.50 | 1.430 | b |
| 2.595 | 1.428 | b |

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.0 - 2.6 μ

TEMPERATURE 291 °K

METHOD not stated

REFERENCE Smakula [1952]

REMARKS References for this Table:

(a) Carvallo, A., Compt. rend., Vol. 126, (1898), p. 728.

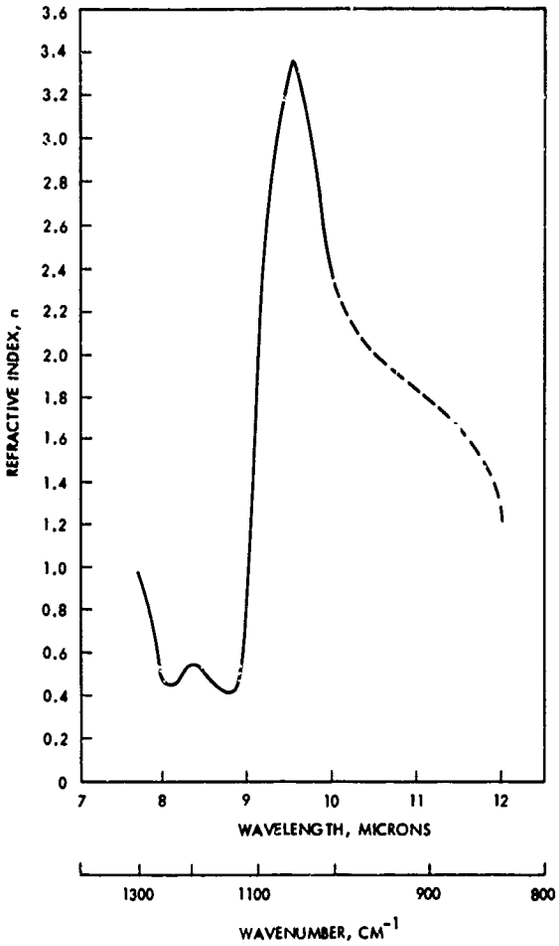
(b) Muller, C. and Wetthauer, A., Z. Phys., Vol. 35, (1933), p. 559.

(c) Sifford, J. W., Proc. Roy. Soc., Vol. 70, (1902), p. 329.

Table 6-13

PARAMETER: Wavelength

MATERIAL: Silica, Fused




FORM Bulk

THICKNESS 6.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7.7 - 12 μ

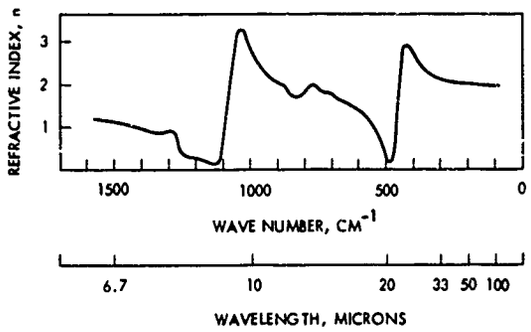
TEMPERATURE ~298 °K

METHOD Reflectance

REFERENCE Cleck (27331)

REMARKS Corning Code 7940 silica

Figure 6-19




THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 6 - 100 μ

TEMPERATURE 298 °K

METHOD Reflectance

REFERENCE Miler (21593, 34239)

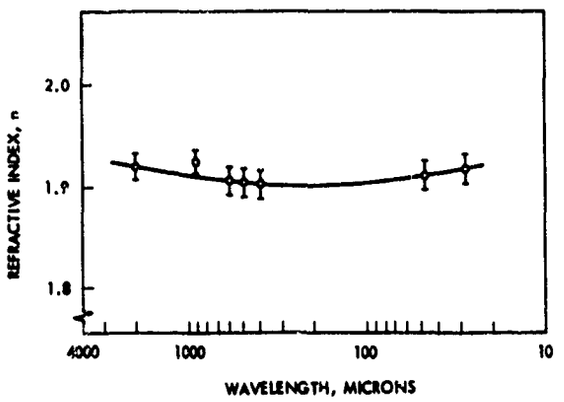
REMARKS

Figure 6-20

Published with permission
Copyright © 1965 Akademie Verlag

PARAMETER: Wavelength

MATERIAL: Silica, Fused




FORM Not stated

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 30 - 2000 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Block, et al. (36747)

REMARKS

Figure 6-21

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 50 | 2.07 |
| 90 | 1.94 |
| 220 | 1.89 |
| 250 | 1.92 |
| 270 | 1.89 |
| 330 | 1.92 |
| 400 | 1.92 |

THICKNESS 50-90 μ 25 mm (Bulk) mm
220-400μ 0.258 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 50 - 400 μ

TEMPERATURE ~298 °K

METHOD Reflection, Interference

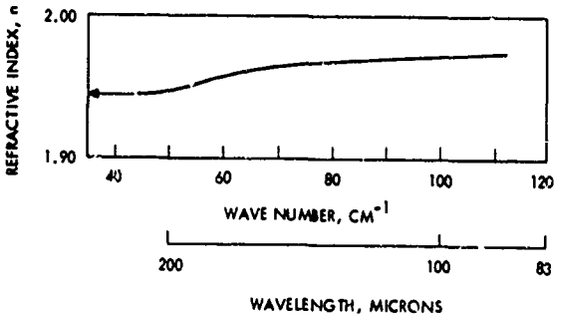
REFERENCE Bogens and Zhukov (35268)

REMARKS

Table 6-14

PARAMETER: Wavelength

MATERIAL: Silica, Fused




Published with permission
Copyright © 1961 Springer-Verlag

FORM Bulk

THICKNESS 0.5 mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 85 - 200 μ

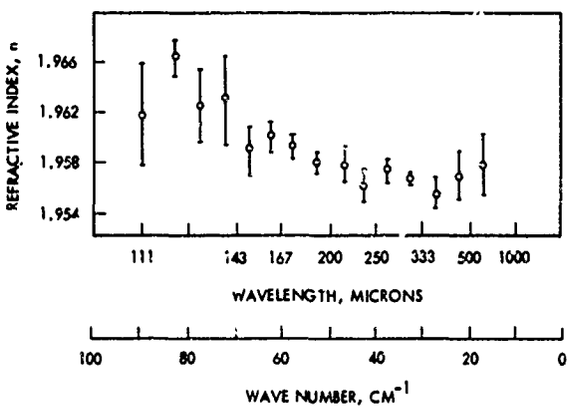
TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Geick (39706)

REMARKS

Figure 6-22




THICKNESS 2.1409 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 111 - 600 μ

TEMPERATURE ~298 °K

METHOD Interference

REFERENCE Randall and Rawcliffe (33251)

REMARKS Infrasil low $H_2O$ quartz

Figure 6-23

PARAMETER: Wavelength

MATERIAL: Silica, Fused

FORM Bulk

THICKNESS 18-, 40 mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 2,000 μ

TEMPERATURE ~298 °K

METHOD Transmission

REFERENCE Dianov and Irisova (41423)

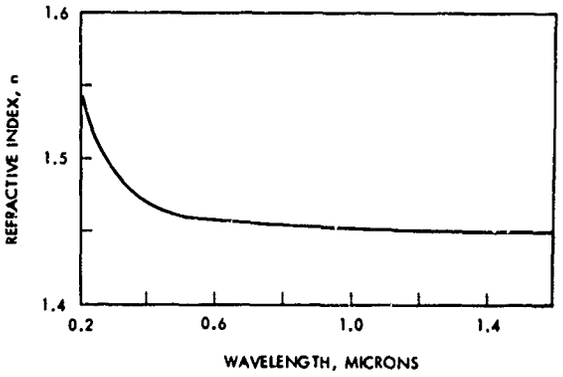
REMARKS Sample consisted of two wedges.

| Wavelength, Microns | Refractive Index, n | Extinction Coefficient, k x $10^3$ |
|---|---|---|
| 2000 | 1.95 ± 0.008 | 0.56 ± 0.06 |

Table 6-15

PARAMETER: Wavelength

MATERIAL: Silica, Fused




FORM Film

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.2 - 1.5 μ

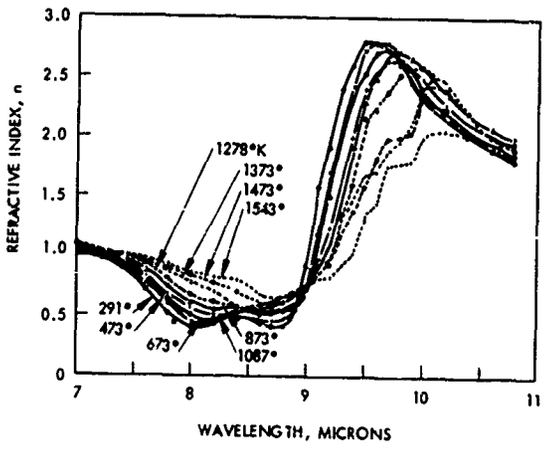
TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Cox, et al. (17066)

REMARKS Film produced by electron bombardment of fused silica, evaporated on fused silica substrate.

Figure 6-24




Published with permission
Copyright © 1956 Springer-Verlag

THICKNESS $5 \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7 - 11 μ

TEMPERATURE 291 - 1543 °K

METHOD Reflection

REFERENCE Neuroth (40354)

REMARKS

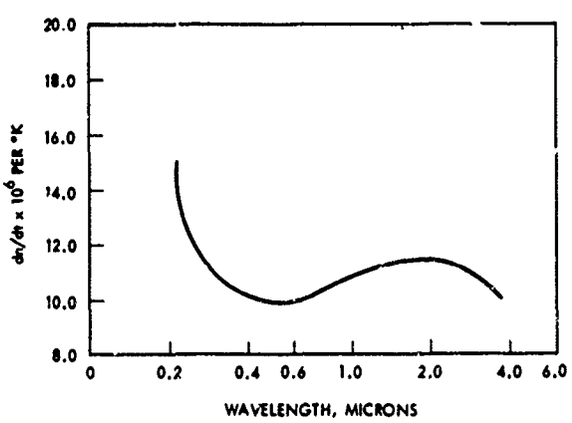
Figure 6-25

**PARAMETER:** Temperature

**MATERIAL:** Silica, Fused

| Wavelength, (Microns) | Refractive Index n 299°K | Refractive Index n 744°K | (dn/dT)/°K x $10^6$ | Refractive Index, n 1101°K | (dn/dT)/°K x $10^6$ |
|---|---|---|---|---|---|
| 0.23021 | 1.52034 | 1.52908 | +19.6 | 1.53524 | +19.3 |
| 0.23783 | 1.51496 | 1.52332 | +18.8 | 1.52985 | +15.6 |
| 0.2407 | 1.51361 | 1.52201 | +18.9 | 1.52832 | +18.3 |
| 0.2465 | 1.50970 | 1.51774 | +18.1 | 1.52391 | +17.7 |
| 0.24827 | 1.50865 | 1.51665 | +18.0 | 1.52289 | +17.8 |
| 0.26520 | 1.50023 | 1.50765 | +16.6 | 1.51351 | +16.5 |
| 0.27528 | 1.49615 | 1.50327 | +16.0 | 1.50899 | +16.0 |
| 0.28035 | 1.49425 | 1.50143 | +16.2 | 1.50691 | +15.8 |
| 0.28936 | 1.49121 | 1.49818 | +15.7 | 1.50358 | +15.4 |
| 0.29673 | 1.48892 | 1.49584 | +15.6 | 1.50112 | +15.2 |
| 0.30215 | 1.48738 | 1.49407 | +15.1 | 1.49942 | +15.0 |
| 0.3130 | 1.48462 | 1.49126 | +14.9 | 1.49641 | +14.7 |
| 0.333415 | 1.48000 | 1.48633 | +14.2 | 1.49135 | +14.1 |
| 0.36502 | 1.47469 | 1.48089 | +14.0 | 1.48563 | +13.6 |
| 0.40466 | 1.46978 | 1.47575 | +13.4 | 1.48033 | +13.2 |
| 0.43584 | 1.46685 | 1.47248 | +12.7 | 1.47716 | +12.9 |
| 0.54607 | 1.46028 | 1.46575 | +12.3 | 1.47004 | +12.2 |
| 0.5780 | 1.45899 | 1.46429 | +11.9 | 1.46870 | +12.1 |
| 1.01398 | 1.45039 | 1.45562 | +11.8 | 1.45960 | +11.5 |
| 1.12866 | 1.44903 | 1.45426 | +11.8 | 1.45820 | +11.4 |
| 1.254 | 1.44772 | 1.45283 | +11.5 | 1.45700 | +11.6 |
| 1.36728 | 1.44635 | 1.45140 | +11.4 | 1.45549 | +11.4 |
| 1.470 | 1.44524 | 1.45[illegible] | +11.4 | 1.45440 | +11.4 |
| 1.52932 | 1.44444 | 1.44961 | +11.6 | 1.45352 | +11.3 |
| 1.660 | 1.44307 | 1.44799 | +11.1 | 1.45174 | +10.8 |
| 1.701 | 1.44230 | 1.44733 | +11.3 | 1.45140 | +11.3 |
| 1.981 | 1.43863 | 1.44361 | +11.2 | 1.44734 | +10.9 |
| 2.262 | 1.43430 | 1.43933 | +11.3 | 1.44306 | +10.9 |
| 2.553 | 1.42949 | 1.43450 | +11.3 | 1.43854 | +11.3 |
| 3.00 | 1.41995 | 1.42495 | +11.2 | 1.42877 | +11.0 |
| 3.245 | 1.41353 | 1.41893 | +12.2 | 1.42243 | +11.1 |
| 3.37[n] | 1.40990 | 1.41501 | +11.5 | 1.41915 | +11.5 |

*Wavelength determination by narrow-bandwidth interference filters.




**FORM** Bulk

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 1.0 - 3.4 μ

**TEMPERATURE** 299 - 1101 °K

**METHOD** Deviation

**REFERENCE** Neu, et al. (40360)

**REMARKS** Corning Code 7940 silica

Table 6-16

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.2 - 4.0 μ

**TEMPERATURE** 293 - 303 °K

**METHOD** Deviation

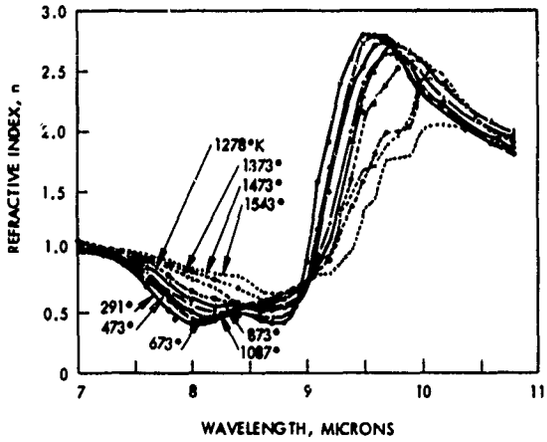
**REFERENCE** Malitson (21758)

**REMARKS**

Figure 6-26

PARAMETER: Temperature

MATERIAL: Silica, Fused




Published with permission
Copyright © 1956 Springer-Verlag

FORM Film

THICKNESS $5 \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7 - 11 μ

TEMPERATURE 291 - 1543 °K

METHOD Reflection

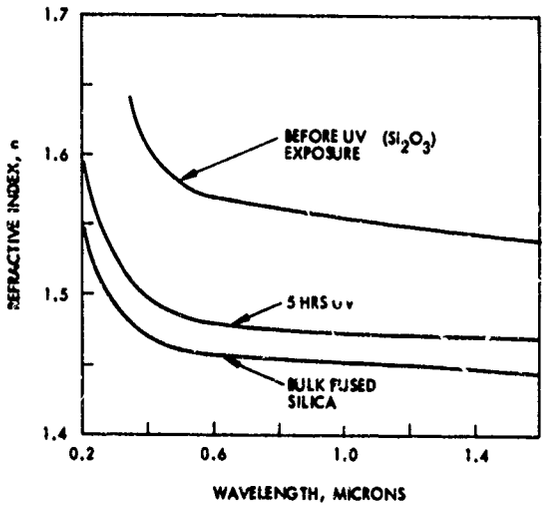
REFERENCE Neuroth (40354)

REMARKS

Figure 6-27

PARAMETER: Radiation (UV)

MATERIAL: Silica, Fused




FORM Film, Amorphous

THICKNESS $(1-5) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.2 - 1.5 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Cox, et al. (17066)

REMARKS Film produced by evaporation of SiO in the presence of oxygen. Data include refractive index before and after ultraviolet irradiation.

Figure 6-28

**PARAMETER:** Radiation (Space)

**MATERIAL:** Silica, Fused

| Wavelength, * (Microns) | Refractive Index, n | | |
|---|---|---|---|
| | Non-irradiated | Irradiated 30 day dose | $\Delta n \times 10^5$ |
| 0.23021 | 1.52034 | 1.52037 | + 3 |
| 0.23783 | 1.51496 | 1.51502 | + 6 |
| 0.2407 | 1.51361 | 1.51363 | + 2 |
| 0.2447 | 1.51081 | 1.51075 | - 6 |
| 0.2465 | 1.50970 | 1.50974 | + 4 |
| 0.24827 | 1.50865 | 1.50869 | + 4 |
| 0.26520 | 1.50023 | 1.50028 | + 5 |
| 0.2700 | 1.49839 | 1.49831 | - 8 |
| 0.27528 | 1.49615 | 1.49616 | + 1 |
| 0.28035 | 1.49425 | 1.49429 | + 4 |
| 0.28936 | 1.49121 | 1.49123 | + 2 |
| 0.2930 | 1.49021 | 1.49023 | + 2 |
| 0.29673 | 1.48892 | 1.48895 | + 3 |
| 0.30215 | 1.48738 | 1.48741 | + 3 |
| 0.3130 | 1.48462 | 1.48460 | - 2 |
| 0.33415 | 1.48000 | 1.47997 | - 3 |
| 0.36502 | 1.47469 | 1.47473 | + 4 |
| 0.40466 | 1.46978 | 1.46981 | + 3 |
| 0.43584 | 1.46685 | 1.46689 | + 4 |
| 0.54607 | 1.46028 | 1.46025 | - 3 |
| 0.5780 | 1.45899 | 1.45900 | + 1 |
| 1.01398 | 1.45039 | 1.45040 | + 1 |
| 1.12866 | 1.44903 | 1.44901 | - 2 |
| 1.254* | 1.44772 | 1.44760 | - 12* |
| 1.36720 | 1.44635 | 1.44633 | - 2 |
| 1.470* | 1.44524 | 1.44513 | - 11* |
| 1.52452 | 1.44444 | 1.44445 | + 1 |
| 1.660* | 1.44307 | 1.44296 | - 11* |
| 1.701 | 1.44230 | 1.44228 | - 2 |
| 1.981* | 1.43863 | 1.43859 | - 4* |
| 2.262* | 1.43430 | 1.43426 | - 4* |
| 2.553* | 1.42949 | 1.42939 | - 10* |
| 3.00* | 1.41995 | 1.41962 | - 33* |
| 3.245* | 1.41353 | 1.41351 | - 2* |
| 3.37* | 1.40990 | 1.40997 | + 7* |

$\delta n = 23 \times 10^{-5}$ (experimental error)

*Wavelength determination by narrow band interference filters.

**FORM** Bulk

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.2 - 3.4 μ

**TEMPERATURE** 299 °K

**METHOD** Deviation

**REFERENCE** Neu, et al. (40360)

**REMARKS** Corning Code 7040 silica.

Radiation simulating 30 day exposure for Apollo mission.

Proton flux: $3 \times 10^{10}$ $cm^{-2}$ $sec^{-1}$ ($\leq 2$ MeV). Electron flux: $2.5 \times 10^{12}$ $cm^{-2}$ $sec^{-1}$ (1 MeV). Ultraviolet: 0.5461 watt-$cm^{-2}$ (0.22 - 0.4 μ) Atmospheric pressure: $P_{min}$ = $10^{-10}$ Torr)

Table 6-17

# CHAPTER 7

## REFRACTIVE INDEX DATA FOR FLUORIDES AND SELECTED CERAMICS

This Chapter provides refractive indices and extinction coefficients for the following fluorides and ceramics which are grouped together on the basis of their high temperature capabilities: Calcium fluoride, magnesium fluoride, aluminum oxide including ruby and sapphire, and magnesium oxide.

# CALCIUM FLUORIDE

## INTRODUCTION

Calcium fluoride offers high and uniform transmission over the range from the ultraviolet region to approximately ten microns (Figures 1-7 and 1-9) and this constant transmission makes this material very desirable for wide spectrum optical applications. Rather pure single crystal calcium fluoride is found in nature and is called "Fluorite" or "Fluorspar." Calcium fluoride of similar purity, but of larger dimensions, has been produced by controlled freezing of purified molten calcium fluoride after an initial scavenging with lead fluoride. Fluorspar is widely used in iron foundry operations, the manufacture of primary aluminum and magnesium, as source of fluorine chemicals, for the production of glass and enamels, and innumerable other uses.

The physical properties of calcium fluoride are summarized in Table 1-1.

## DATA

A list of refractive index data for calcium fluoride is provided in Table 7-1 and the temperature range of the data is plotted in Figure 7-1. The wavelength dependence of the refractive index and some extinction coefficients for bulk single crystal material are presented in Figures 7-2 to 7-9 and Tables 7-2 to 7-6 and for polycrystalline material in Figure 7-10 and Tables 7-7 and 7-8. The data reveal good agreement in refractive index is discernible between single and polycrystalline material. Only in the "Reststrahlen" region of the spectrum (near 38 microns) is there a major disagreement in refractive index between authors. The temperature dependence of the refractive index is covered by Figures 2-3 and 7-11 as well as Tables 7-9 and 7-10.

PRECEDING PAGE BLANK

Table 7-1. List of Calcium Fluoride Data

| Figure | Table | n, k | Form | Crystal | Wavelength (Microns) From | Wavelength (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| | 7-2 | n | Bulk | Single | 0.75 | 1.1 | | Wavelength |
| | 7-3 | n | Bulk | Single | 0.8 | 9.0 | | Wavelength |
| | 7-4 | n | Bulk | Single | 0.9 | 9.4 | | Wavelength |
| | 7-5 | n | Bulk | Single | 0.8 | 9.8 | | Wavelength |
| 7-2 | | n | Bulk | Single | 1 | 10 | | Wavelength |
| | 7-6 | n | Bulk | Single | 0.85 | 9.7 | | Wavelength |
| 7-3 | | k | Bulk | Single | 6 | 9 | | Wavelength |
| 7-4 | | n, k | Bulk | Single | 15 | 48 | | Wavelength |
| 7-5 | | n, k | Bulk | Single | 34 | 43 | | Wavelength |
| 7-6 | | n | Bulk | Single | 10 | 80 | | Wavelength |
| 7-7 | | k | Bulk | Single | 10 | 80 | | Wavelength |
| 7-8 | | n | Bulk | Single | 8 | 15 | | Wavelength |
| 7-9 | | n | Bulk | Single | 55 | 400 | 80, 300°K | Wavelength |
| | 7-7 | n | Bulk | Polycryst. | 0.59 | 5.3 | | Wavelength |
| | 7-8 | n | Bulk | Polycryst. | 1 | 11 | | Wavelength |
| 7-10 | | n | Bulk | Polycryst. | 1 | 11 | | Wavelength |
| | 7-9 | dn/dT | Bulk | Single | 0.9 | 6.5 | 330-354°K | Temperature |
| | 7-10 | dn/dT | Bulk | Single | 0.85 | 9.7 | 292°K | Temperature |
| 7-11 | | n | Bulk | Single | 55 | 400 | 80, 300°K | Temperature |

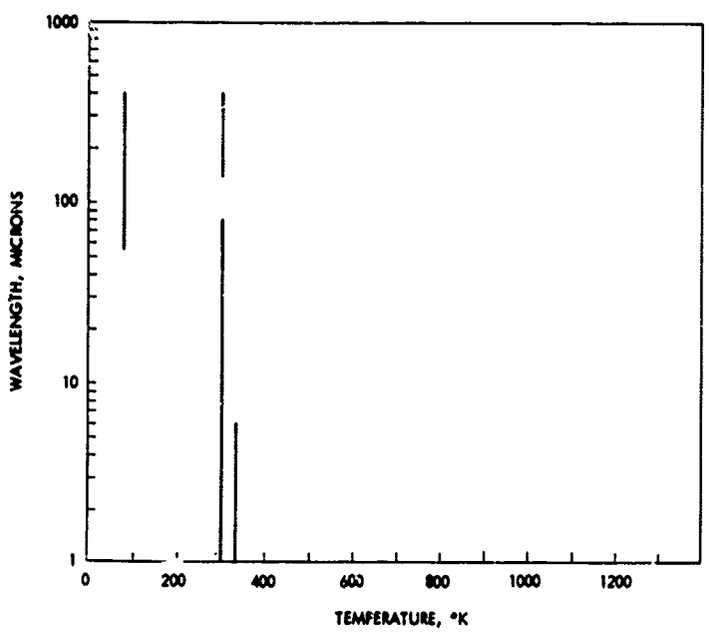



Figure 7-1. Wavelength and Temperature Range of Calcium Fluoride Data

PARAMETER: Wavelength

MATERIAL: Calcium Fluoride

FORM: Bulk (probably single crystal)

THICKNESS: Not stated mm

RAY: ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH: 0.75 - 1.1 μ

TEMPERATURE: 293 °K

METHOD: Not stated

REFERENCE: Harting [1948]

REMARKS:

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 0.750 | 1.43114 | 0.940 | 1.42935 |
| 0.760 | 1.43102 | 0.950 | 1.42927 |
| 0.770 | 1.43090 | 0.960 | 1.42920 |
| 0.780 | 1.43079 | 0.970 | 1.42913 |
| 0.790 | 1.43068 | 0.930 | 1.42906 |
| 0.800 | 1.43057 | 0.990 | 1.42899 |
| 0.810 | 1.43047 | 1.000 | 1.42892 |
| 0.820 | 1.43037 | 1.010 | 1.42885 |
| 0.830 | 1.43027 | 1.020 | 1.42879 |
| 0.840 | 1.43018 | 1.030 | 1.42872 |
| 0.850 | 1.43008 | 1.040 | 1.42866 |
| 0.860 | 1.42999 | 1.050 | 1.42859 |
| 0.870 | 1.42990 | 1.060 | 1.42853 |
| 0.880 | 1.42982 | 1.070 | 1.42847 |
| 0.890 | 1.42974 | 1.080 | 1.42841 |
| 0.900 | 1.42966 | 1.090 | 1.42835 |
| 0.910 | 1.42958 | 1.100 | 1.42829 |
| 0.920 | 1.42950 | 1.110 | 1.42823 |
| 0.930 | 1.42942 | 1.120 | 1.42817 |

Table 7-2

THICKNESS: Not stated mm

RAY: ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH: 0.8 - 9.0 μ

TEMPERATURE: 293 °K

METHOD: Not stated

REFERENCE: Smakula [1952]

REMARKS: Data taken from Kohlrausch [1943]

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 0.80 | 1.430563 | 3.0 | 1.41793 |
| 0.90 | 1.429651 | 3.5 | 1.41412 |
| 1.00 | 1.428923 | 4.0 | 1.40971 |
| 1.2 | 1.427760 | 4.5 | 1.40469 |
| 1.4 | 1.426772 | 5.0 | 1.39901 |
| 1.6 | 1.425833 | 6.0 | 1.38562 |
| 1.8 | 1.424885 | 7.0 | 1.36932 |
| 2.0 | 1.423895 | 8.0 | 1.34988 |
| 2.3 | 1.422294 | 9.0 | 1.32685 |
| 2.6 | 1.420525 | | |

Table 7-3

**PARAMETER:** Wavelength

**MATERIAL:** Calcium Fluoride

| Wavelength (Microns) | Refractive Index, n | Wavelength (Microns) | Refractive Index, n |
|---|---|---|---|
| 0.48400 | 1.42980 | 2.800 | 1.41923 |
| 1.0140 | 1.42884 | 2.880 | 1.41890 |
| 1.08304 | 1.42843 | 2.9466 | 1.41825 |
| 1.1000 | 1.42833 | 3.0500 | 1.41750 |
| 1.1786 | 1.42789 | 3.0980 | 1.41714 |
| 1.250 | 1.42752 | 3.2413 | 1.41610 |
| 1.3756 | 1.42689 | 3.4000 | 1.41487 |
| 1.4733 | 1.42642 | 3.5359 | 1.41376 |
| 1.5715 | 1.42596 | 3.8306 | 1.41119 |
| 1.680 | 1.42558 | 4.000 | 1.40963 |
| 1.7680 | 1.42502 | 4.1252 | 1.40847 |
| 1.8400 | 1.42468 | 4.2500 | 1.40722 |
| 1.8888 | 1.42454 | 4.4000 | 1.40568 |
| 1.900 | 1.42439 | 4.6000 | 1.40357 |
| 1.9153 | 1.42431 | 4.7146 | 1.40233 |
| 1.9644 | 1.42407 | 4.8000 | 1.40130 |
| 2.0582 | 1.42360 | 5.000 | 1.39908 |
| 2.0626 | 1.42357 | 5.3036 | 1.39522 |
| 2.1608 | 1.42306 | 5.8932 | 1.38712 |
| 2.250 | 1.42258 | 6.4825 | 1.37824 |
| 2.3571 | 1.42198 | 7.0718 | 1.36805 |
| 2.450 | 1.42143 | 7.6612 | 1.35675 |
| 2.5537 | 1.42080 | 8.2505 | 1.34440 |
| 2.6519 | 1.42018 | 8.8398 | 1.33079 |
| 2.700 | 1.41988 | 9.4291 | 1.31605 |
| 2.750 | 1.41956 | | |

**FORM** Bulk

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.9 - 9.4 μ

**TEMPERATURE** 293 °K

**METHOD** Not stated

**REFERENCE** Ballard (12539)

**REMARKS**

Table 7-4

| Wavelength, (Microns) | Refractive Index n | Wavelength, (Microns) | Refractive Index n |
|---|---|---|---|
| 0.80 | 1.44052 | 4.60 | 1.40154 |
| 0.82 | 1.44032 | 4.80 | 1.40130 |
| 0.84 | 1.44013 | 5.00 | 1.39895 |
| 0.86 | 1.42995 | 5.20 | 1.39650 |
| 0.88 | 1.42977 | 5.40 | 1.39394 |
| 0.90 | 1.42961 | 5.60 | 1.39127 |
| 0.92 | 1.42945 | 5.80 | 1.38849 |
| 0.94 | 1.42930 | 6.00 | 1.38559 |
| 0.96 | 1.42915 | 6.20 | 1.38258 |
| 0.98 | 1.42901 | 6.40 | 1.37945 |
| 1.00 | 1.42888 | 6.60 | 1.37620 |
| 1.20 | 1.42771 | 6.80 | 1.37282 |
| 1.40 | 1.42672 | 7.00 | 1.36932 |
| 1.60 | 1.42579 | 7.20 | 1.36569 |
| 1.80 | 1.42484 | 7.40 | 1.36193 |
| 2.00 | 1.42385 | 7.60 | 1.35804 |
| 2.20 | 1.42285 | 7.80 | 1.35401 |
| 2.40 | 1.42168 | 8.00 | 1.34983 |
| 2.60 | 1.42049 | 8.20 | 1.34552 |
| 2.80 | 1.41921 | 8.40 | 1.34106 |
| 3.00 | 1.41785 | 8.60 | 1.33645 |
| 3.20 | 1.41639 | 8.80 | 1.33169 |
| 3.40 | 1.41480 | 9.00 | 1.32677 |
| 3.60 | 1.41320 | 9.20 | 1.32168 |
| 3.80 | 1.41147 | 9.40 | 1.31643 |
| 4.00 | 1.40963 | 9.60 | 1.31101 |
| 4.20 | 1.40770 | 9.80 | 1.30541 |
| 4.40 | 1.40567 | | |

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.8 - 9.8 μ

**TEMPERATURE** 297 °K

**METHOD** Deviation

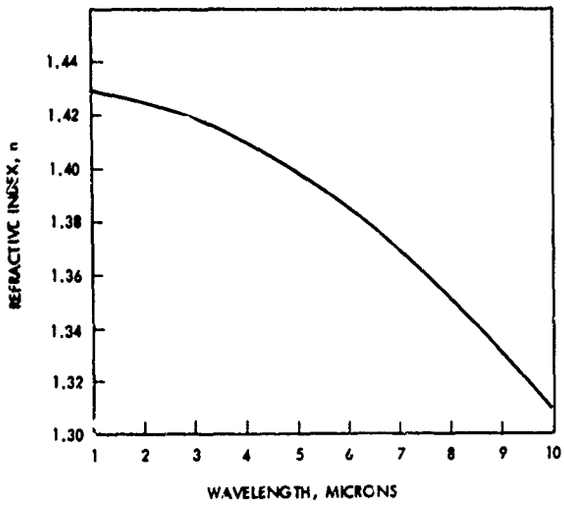
**REFERENCE** Malitson (39194)

**REMARKS** Computed refractive index, based on observed data.

Table 7-5

PARAMETER: Wavelength

MATERIAL: Calcium Fluoride




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 10 μ

TEMPERATURE 297 °K

METHOD Deviation

REFERENCE Malitson (39194)

REMARKS Synthetic crystal

Figure 7-2

| Wavelength, (Microns) | Computed Index, n | Residual [(Observed-Computed) x $10^5$] Material: Synthetic o-c | Residual [(Observed-Computed) x $10^5$] Material: Natural o-c |
|---|---|---|---|
| 0.85212 | 1.43002 | -1 | +4 |
| 0.8944 | 1.42966 | 0 | +1 |
| 1.01398 | 1.42879 | -2 | 0 |
| 1.3622 | 1.42691 | +1 | +8 |
| 1.39506 | 1.42675 | +1 | +6 |
| 1.52952 | 1.42612 | +4 | +4 |
| 1.7012 | 1.42531 | +2 | +4 |
| 1.81307 | 1.42478 | 0 | +9 |
| 1.97009 | 1.42401 | +3 | +3 |
| 2.1526 | 1.42306 | -1 | +1 |
| 2.32542 | 1.42212 | +3 | +4 |
| 2.4374 | 1.42147 | 0 | +2 |
| 3.3026 | 1.41561 | 0 | +3 |
| 3.422 | 1.41467 | +2 | +2 |
| 3.5070 | 1.41398 | -1 | +2 |
| 3.7067 | 1.41229 | +2 | +2 |
| 4.258 | 1.40713 | +4 | +4 |
| 5.01882 | 1.39873 | +1 | +5 |
| 5.3034 | 1.39520 | +3 | +3 |
| 5.6140 | 1.39536 | +5 | +5 |
| 6.238 | 1.38200 | -6 | 0 |
| 6.63306 | 1.37565 | 0 | +1 |
| 6.8559 | 1.37186 | -8 | +2 |
| 7.268 | 1.36443 | +2 | +7 |
| 7.4644 | 1.36070 | +5 | +6 |
| 8.662 | 1.33500 | -4 | +3 |
| 9.724 | 1.30756 | +1 | +5 |

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 10 μ

TEMPERATURE 297 °K

METHOD Deviation

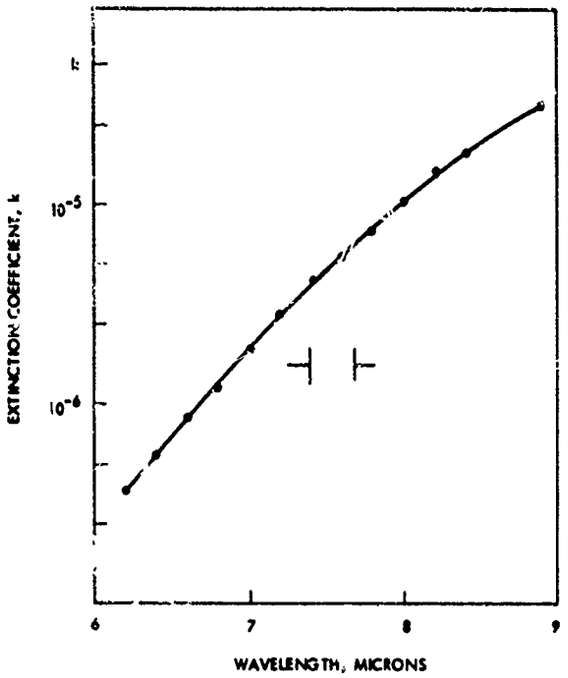
REFERENCE Malitson (39194)

REMARKS Comparison of natural and synthetic single crystals

Table 7-6

**PARAMETER:** Wavelength

**MATERIAL:** Calcium Fluoride




**FORM** Bulk, Single Crystal

**THICKNESS** 111.7(6-9μ), 8 (15-48μ) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 6 - 48 μ

**TEMPERATURE** ~298 °K

**METHOD** 6-9μ-Transmission; 15-48μ Reflection.

**REFERENCE** Heilmann (40178)

**REMARKS** Improved results over earlier work, reported by Heilmann [1961]

Figure 7-3

Published with permission
Copyright © 1963 Springer-Verlag

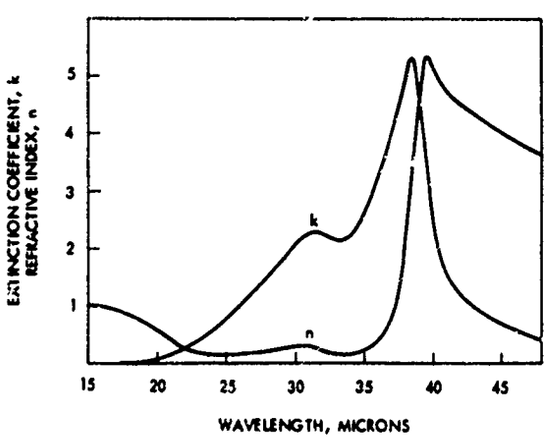



Figure 7-4

**PARAMETER:** Wavelength (Cont'd from preceding page) **MATERIAL:** Calcium Flouride

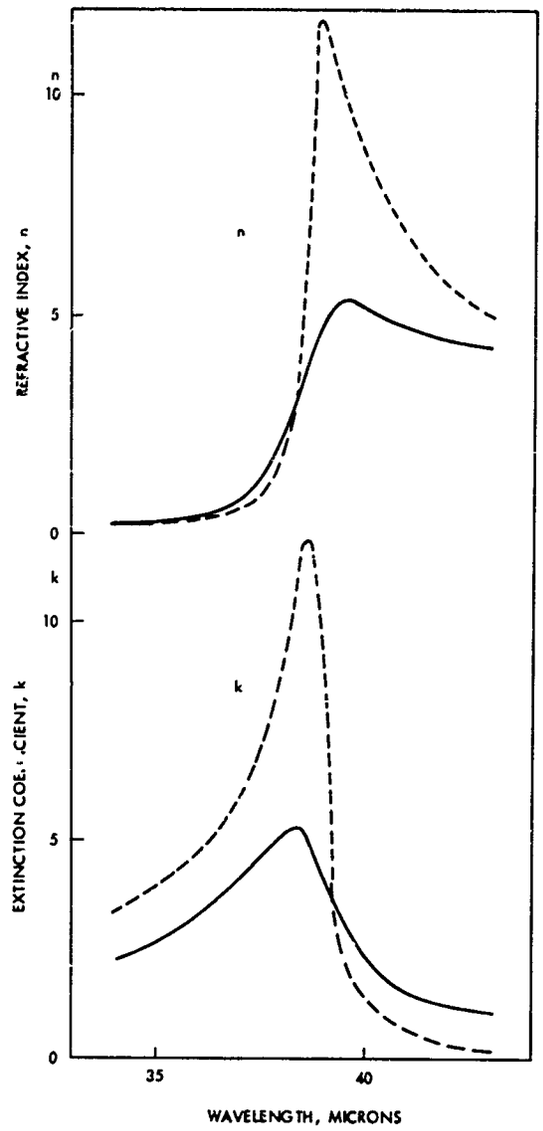
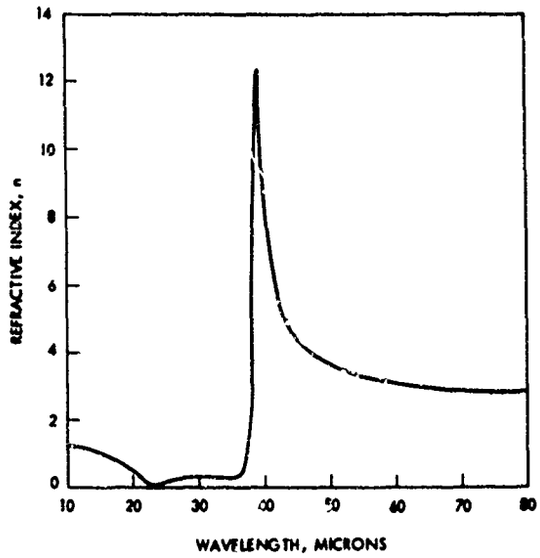



Figure 7-5

Note: ----- Results of Kaiser, et al (40176).

PARAMETER: Wavelength

MATERIAL: Calcium Fluoride




FORM Bulk, Single Crystal

THICKNESS 0.1 - 5 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 10 - 80 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Kaiser, et al. (40176)

REMARKS

Figure 7-6

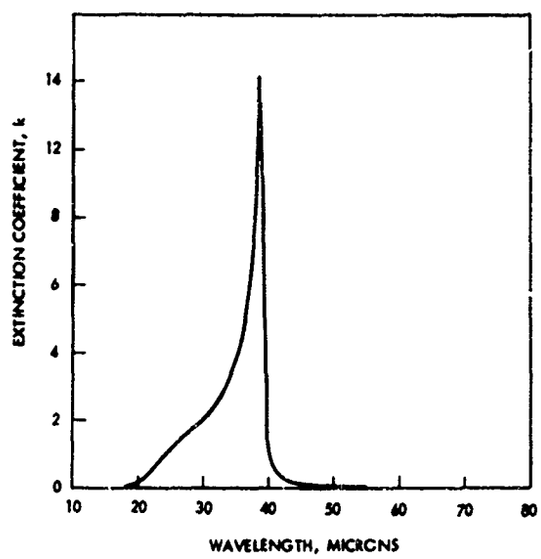
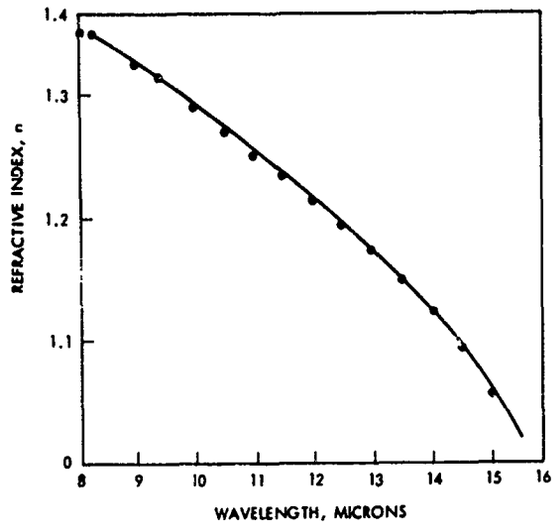



Figure 7-7

**PARAMETER:** Wavelength

**MATERIAL:** Calcium Fluoride




**FORM** Bulk, Single Crystal

**THICKNESS** 0.025 - 0.050 mm

**RAY** ORDINARY ☒ , EXTRAORDINARY ☐

**WAVELENGTH** 8 - 15 μ

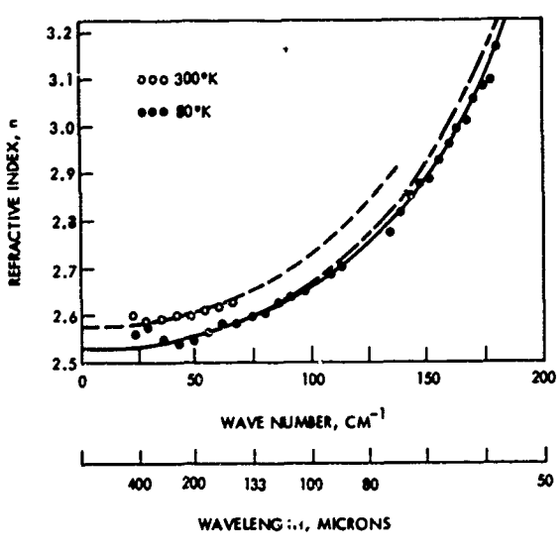
**TEMPERATURE** ~298 °K

**METHOD** Interference

**REFERENCE** Ramadier - Delbès (39712)

**REMARKS**

Figure 7-8




**THICKNESS** 0.3 - 10 mm

**RAY** ORDINARY ☒ , EXTRAORDINARY ☐

**WAVELENGTH** 55 - 400 μ

**TEMPERATURE** 80, 300 °K

**METHOD** Interference

**REFERENCE** Bosomworth (029681)

**REMARKS** Principal impurity 10-100 ppm of iron. Lines are based on dielectric constant of an infinite harmonic fluorite lattice.

Figure 7-9

PARAMETER: Wavelength

MATERIAL: Calcium Fluoride

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.588 | 1.4339 |
| 1.014 | 1.4289 |
| 1.529 | 1.4262 |
| 1.970 | 1.4241 |
| 2.325 | 1.4222 |
| 2.674 | 1.4200 |
| 3.303 | 1.4157 |
| 4.258 | 1.4072 |
| 4.59 | 1.4034 |
| 5.303 | 1.3952 |

FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.59 - 5.3 μ

TEMPERATURE ~298 °K

METHOD Not stated

REFERENCE Type IRG 12 material

REMARKS

Table 7-7

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.000 | 1.4289 | 5.7500 | 1.3892 |
| 1.2500 | 1.4275 | 6.0000 | 1.3856 |
| 1.5000 | 1.4263 | 6.2500 | 1.3818 |
| 1.7500 | 1.4251 | 6.5000 | 1.3778 |
| 2.0000 | 1.4239 | 6.7500 | 1.3737 |
| 2.2500 | 1.4226 | 7.0000 | 1.3693 |
| 2.5000 | 1.4211 | 7.2500 | 1.3648 |
| 2.7500 | 1.4196 | 7.5000 | 1.3600 |
| 3.0000 | 1.4179 | 7.7500 | 1.3550 |
| 3.2500 | 1.4161 | 8.0000 | 1.3498 |
| 3.5000 | 1.4141 | 8.2500 | 1.3445 |
| 3.7500 | 1.4120 | 8.5000 | 1.3388 |
| 4.0000 | 1.4097 | 8.7500 | 1.3330 |
| 4.2500 | 1.4072 | 9.0000 | 1.3269 |
| 4.50000 | 1.4047 | 9.2500 | 1.3206 |
| 4.7500 | 1.4019 | 9.5000 | 1.3141 |
| 5.0000 | 1.3990 | 9.7500 | 1.3073 |
| 5.2500 | 1.3959 | 10.0000 | 1.3002 |
| 5.5000 | 1.3926 | 11.0000 | 1.2694 |

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 11 μ

TEMPERATURE 298 °K

METHOD Not stated

REFERENCE Kodak [1967]

REMARKS ITRAN-3 material

Table 7-8

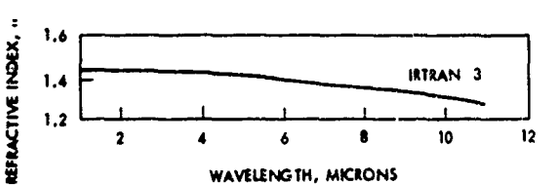



Figure 7-10

**PARAMETER:** Temperature

**MATERIAL:** Calcium Fluoride

| Wavelength (Microns) | Temperature Coefficient, $-(dn/dT) \times 10^6$ | Mean Temperature, °K |
|---|---|---|
| 0.900 | 10.31 | 333.1 |
| 1.200 | 10.40 | 333.1 |
| 1.25 | 10.29 | 333.2 |
| 1.30 | 10.18 | 333.5 |
| 2.0 | 9.32 | 333.5 |
| 3.16 | 8.81 | 332.6 |
| 4.2 | 8.31 | 332.8 |
| 5.3 | 8.21 | 332.2 |
| 6.5 | 7.87 | 330.0 |

**FORM** Bulk, Single Crystal

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.9 - 6.5 μ

**TEMPERATURE** 330 - 335 °K

**METHOD** Not stated

**REFERENCE** Smakula [1952]

**REMARKS** Data taken from Liebreich [1911]

Table 7-9

| Wavelength, (Microns) | Computed Index, n | Temperature Coefficient, $-(dn/dT) \times 10^6$ |
|---|---|---|
| 0.85212 | 1.43002 | 10.6 |
| 0.8944 | 1.42966 | 10.6 |
| 1.01398 | 1.42879 | 10.5 |
| 1.39506 | 1.42675 | 9.9 |
| 1.52952 | 1.42612 | 9.6 |
| 1.7012 | 1.42531 | 9.4 |
| 1.81307 | 1.42478 | 9.1 |
| 1.97009 | 1.42401 | 8.9 |
| 2.1526 | 1.42306 | 8.7 |
| 2.32542 | 1.42212 | 8.5 |
| 2.4374 | 1.42147 | 8.5 |
| 3.3026 | 1.41561 | 8.2 |
| 3.422 | 1.41467 | 8.1 |
| 3.5070 | 1.41398 | 8.0 |
| 3.7067 | 1.41229 | 7.8 |
| 4.258 | 1.40713 | 7.5 |
| 5.01882 | 1.39873 | 7.3 |
| 5.3034 | 1.39520 | 7.2 |
| 6.0140 | 1.38539 | 7.0 |
| 6.238 | 1.38200 | 7.0 |
| 6.63306 | 1.37565 | 6.9 |
| 6.8559 | 1.37186 | 6.7 |
| 7.268 | 1.36443 | 6.5 |
| 7.4644 | 1.36070 | 6.4 |
| 8.662 | 1.33500 | 6.0 |
| 9.724 | 1.30756 | 5.6 |

**THICKNESS** NA (Prism) mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.85 - 9.7 μ

**TEMPERATURE** 292 °K

**METHOD** Deviation

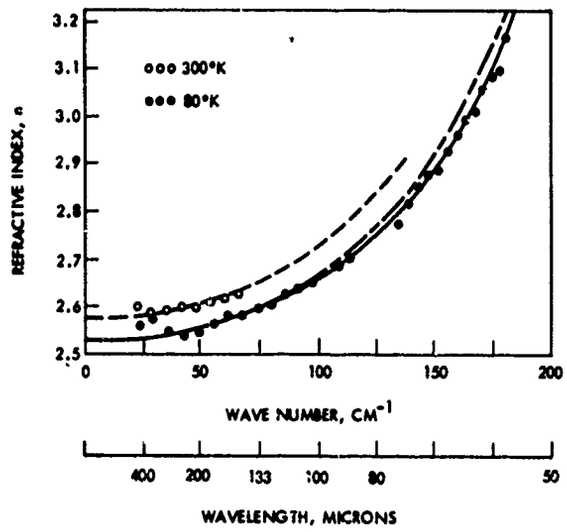
**REFERENCE** Malitson (39194)

**REMARKS** Synthetic single crystal.

Table 7-10

**PARAMETER:** Temperature

**MATERIAL:** Calcium Fluoride




| | |
|---|---|
| **FORM** | Bulk, Single Crystal |
| **THICKNESS** | 0.3 - 10 mm |
| **RAY** | ORDINARY ☒, EXTRAORDINARY ☐ |
| **WAVELENGTH** | 55 - 400 μ |
| **TEMPERATURE** | 80, 300 °K |
| **METHOD** | Interference |
| **REFERENCE** | Bosomworth (29681) |
| **REMARKS** | Principal impurity 10-100 ppm of iron. Lines are based on dielectric constant of an infinite harmonic fluorite lattice. |

Figure 7-11

## MAGNESIUM FLUORIDE

### INTRODUCTION

Magnesium fluoride is prepared by the reaction of magnesium oxide with hydrofluoric acid and as a byproduct from the reduction of metal fluorides with magnesium in the manufacture of some metals. Magnesium fluoride is used as flux in the metallurgy of magnesium metal, as flux for porcelain and pottery, as phosphor in cathode ray screens, as coating agent for titanium pigments, and in optics as window material and antireflection coating on lenses.

The optical transmission of polycrystalline magnesium fluoride is shown in Figure 1-9, and its physical properties are listed in Table 1-1.

### DATA

Refractive index data for magnesium fluoride are listed in Table 7-11 and consist only of one set of data for polycrystalline material (Figure 7-12 and Table 7-12) and one data point for magnesium fluoride film (Table 7-13). This apparent lack of data in the literature does not permit a comparison of results.

Table 7-11. List of Magnesium Fluoride Data

| Figure | Table | n, k | Form | Crystal | Wavelength (Microns) | | Parameter |
|---|---|---|---|---|---|---|---|
| | | | | | From | To | |
| | 7-12 | n | Bulk | Polycryst | 1.0 | 6.75 | Wavelength |
| 7-12 | | n | Bulk | Polycryst | 1 | 9 | Wavelength |
| | 7-13 | n | Film | * | 2.0 | 2.0 | Wavelength |

*Not Stated

PARAMETER: Wavelength

MATERIAL: Magnesium Fluoride

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.0000 | 1.3778 | 4.0000 | 1.3526 |
| 1.2500 | 1.3763 | 4.2500 | 1.3492 |
| 1.5000 | 1.3749 | 4.5000 | 1.3455 |
| 1.7500 | 1.3735 | 4.7500 | 1.3416 |
| 2.0000 | 1.3720 | 5.0000 | 1.3374 |
| 2.2500 | 1.3702 | 5.2500 | 1.3329 |
| 2.5000 | 1.3683 | 5.5000 | 1.3282 |
| 2.7500 | 1.3663 | 5.7500 | 1.3232 |
| 3.0000 | 1.3640 | 6.0000 | 1.3179 |
| 3.2500 | 1.3614 | 6.2500 | 1.3122 |
| 3.5000 | 1.3587 | 6.5000 | 1.3063 |
| 3.7500 | 1.3558 | 6.7500 | 1.3000 |

FORM Bulk, Polycrystalline

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 9 μ

TEMPERATURE 298 °K

METHOD Not stated

REFERENCE Kodak [1967]

REMARKS IRTRAN-1 material

Table 7-12

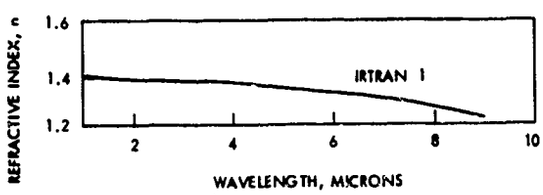



Figure 7-12

PARAMETER: Wavelength

MATERIAL: Magnesium Fluoride

| Wavelength, Microns | Refractive Index, $n_o$ |
|---|---|
| 2 | 1.36 |

FORM Film

THICKNESS ~5 x $10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH ~2 μ

TEMPERATURE ~298 °K

METHOD Transmission

REFERENCE Jenness (40476)

REMARKS Evaporated coating on fused silica substrate. Extraordinary ray neglected.

Table 7-13

## ALUMINUM OXIDE – CORUNDUM – SAPPHIRE – RUBY

### INTRODUCTION

Corundum is a naturally-occurring $\alpha$-alumina, ($Al_2O_3$), which crystallizes in the hexagonal form. Pure corundum is fully transparent and water-white, and is called "white sapphire." Corundum for optical applications is generally synthesized and called "sapphire." Corundum crystals containing from approximately 0.04 to 5 percent chromic oxide in their lattices are called "ruby." The ruby's applications in optics are mostly in laser technology. The synthesis of sapphire is commonly performed by means of the Verneuil or flame fusion process which is based on the fusion of the aluminum oxide with heat from a hydrogen-oxygen source and growth at a controlled temperature of approximately 2300°K. The light transmission through sapphire is shown in Figure 1-8 and shows a useful region between 0.2 and 5 microns. The infrared optical properties of corundum, sapphire and ruby are essentially identical, [Ref. Haefele (9762)].

Physical properties of sapphire are summarized in Table 1-1. Uses for aluminum oxide include gems, jewel bearings, luminescent materials, abrasives and optics.

### DATA

A list of data presentations for aluminum oxide is offered in Table 7-14 and the wavelength- and temperature coverage is plotted in Figure 7-13. The spectral dependence of the refractive index of bulk corundum, sapphire and ruby is shown in Figures 7-14 to 7-22 and Tables 7-15 to 7-17 for ordinary and extraordinary rays with inclusion of some extinction coefficients. The data show good agreement among authors and materials. Data for amorphous films are presented in Figures 7-23 and 7-24 with fair agreement of the sparse data with bulk data. Table 7-18 gives refractive index data as a function of wavelength and anodizing potential, and it is apparent

PRECEDING PAGE BLANK

that low anodizing potentials give high readings — more nearly resembling the metal than the oxide. The temperature dependence of the refractive index is covered by Figures 7-25 and 7-26 as well as Tables 7-19 and 7-20.

Table 7-14. List of Aluminum Oxide Data

| Figure | Table | n, k | Form | Crystal | Wavelength (Microns) From | Wavelength (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 7-14 | | n, k | Bulk | Corundum | 9 | 33 | 293°K | Wavelength |
| 7-15 | | n, k | Bulk | Corundum | 9 | 33 | 1773°K | Wavelength |
| 7-16 | | n | Bulk | Sapphire | 0.3 | 5.6 | | Wavelength |
| | 7-15 | n | Bulk | Sapphire | 2.0 | 3.6 | | Wavelength |
| 7-17 | | n | Bulk | Sapphire | 58 | 500 | O-ray | Wavelength |
| 7-18 | | n | Bulk | Sapphire | 58 | 500 | E-ray | Wavelength |
| 7-19 | | n | Bulk | Sapphire | 180 | 500 | O & E-rays | Wavelength |
| | 7-16 | n | Bulk | Sapphire | 58 | 500 | O & E-rays | Wavelength |
| 7-20 | | n | Bulk | Sapphire | 112 | 300 | | Wavelength |
| | 7-17 | n | Bulk | Sapphire | 167 | 500 | O & E-rays | Wavelength |
| 7-21 | | n, k | Bulk | Ruby | 6 | 33 | O-ray | Wavelength |
| 7-22 | | n, k | Bulk | Ruby | 6 | 33 | E-ray | Wavelength |
| | 7-1[illegible] | n | Film | Amorphous | 1.5 | 15 | | Wavelength |
| 7-23 | | n | Film | Amorphous | 0.2 | 1.6 | 318°K, 573°K | Wavelength |
| 7-24 | | n | Film | Amorphous | 15 | 57 | | Wavelength |
| 7-25 | | n, k | Bulk | Corundum | 9 | 33 | 293°K | Temperature |
| 7-26 | | n, k | Bulk | Corundum | 9 | 33 | 1773°K | Temperature |
| | 7-19 | n | Bulk | Sapphire | 0.56 | 4.0 | 296 — 1973°K | Temperature |
| | 7-20 | dn/dT | Bulk | Sapphire | 4 | 4 | 292 — 297°K | Temperature |

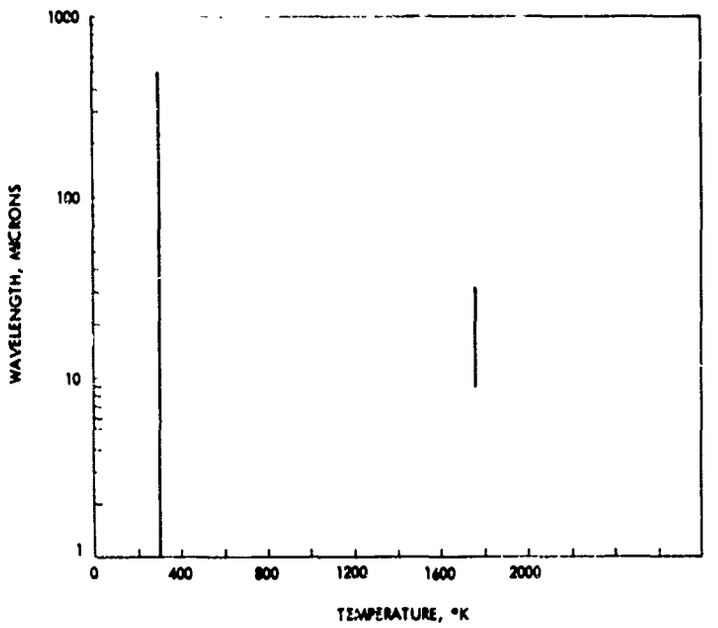
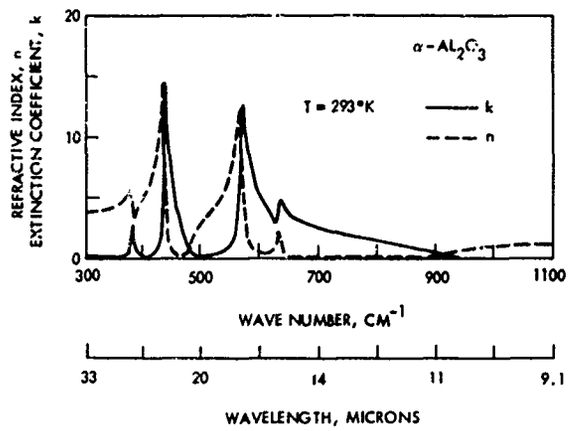



Figure 7-13. Wavelength and Temperature Range of Aluminum Oxide Data

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide-Corundum




Published with permission
Copyright © 1966 Masson et Cie.

FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 9 – 33 μ

TEMPERATURE 293, 1773 °K

METHOD Reflection

REFERENCE Piriou (29797)

REMARKS

Figure 7-14

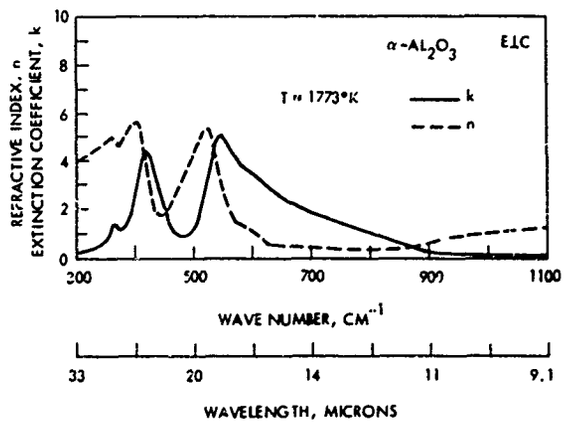
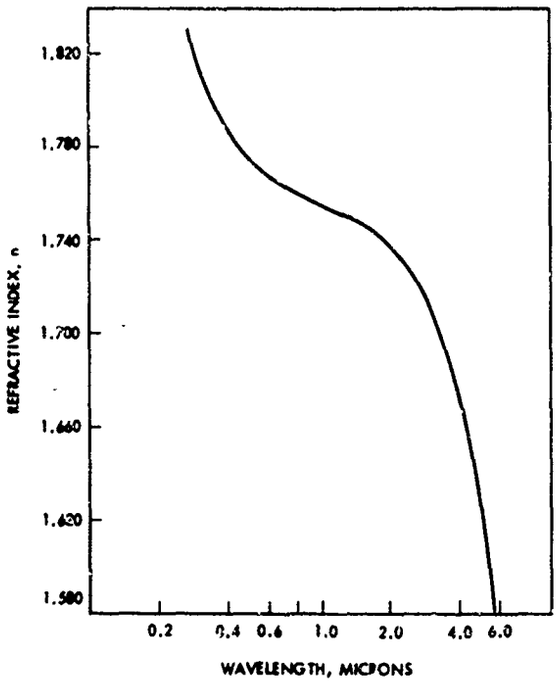



Figure 7-15

PRECEDING PAGE BLANK

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide-Sapphire




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.3 – 5.6 μ

TEMPERATURE 297 °K

METHOD Deviation

REFERENCE Malitson (17008)

REMARKS

Figure 7-16

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 2.0 | 1.65 |
| 3.6 | 1.60 |

THICKNESS 1.6, 3.2 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2.0, 3.6 μ

TEMPERATURE ~298 °K

METHOD Transmission

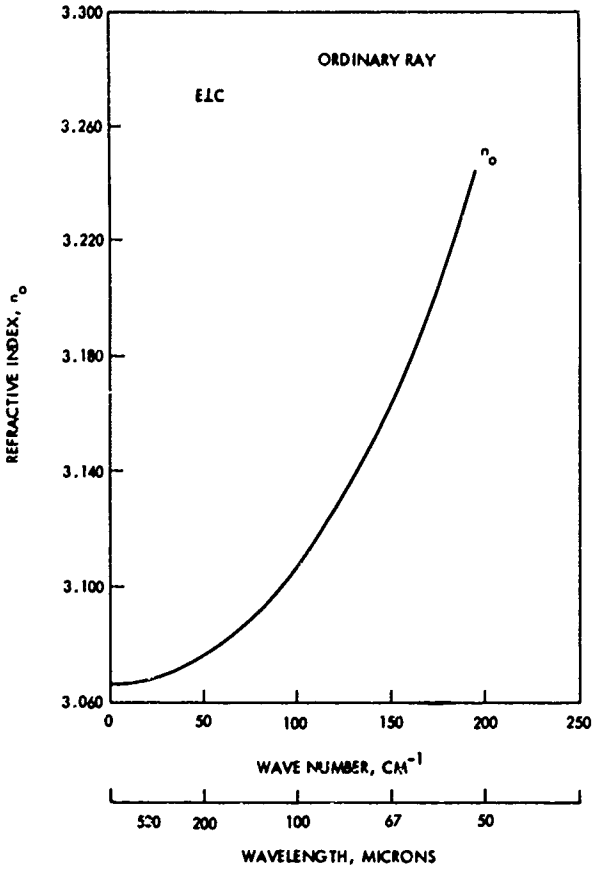
REFERENCE Jenness (40476)

REMARKS Values estimated from LiF coating data

Table 7-15

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide-Sapphire




FORM Bulk, Single Crystal

THICKNESS 1.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 58 - 500 μ

TEMPERATURE 301 °K

METHOD Interference

REFERENCE Russell & Bell (28755)

REMARKS

Figure 7-17

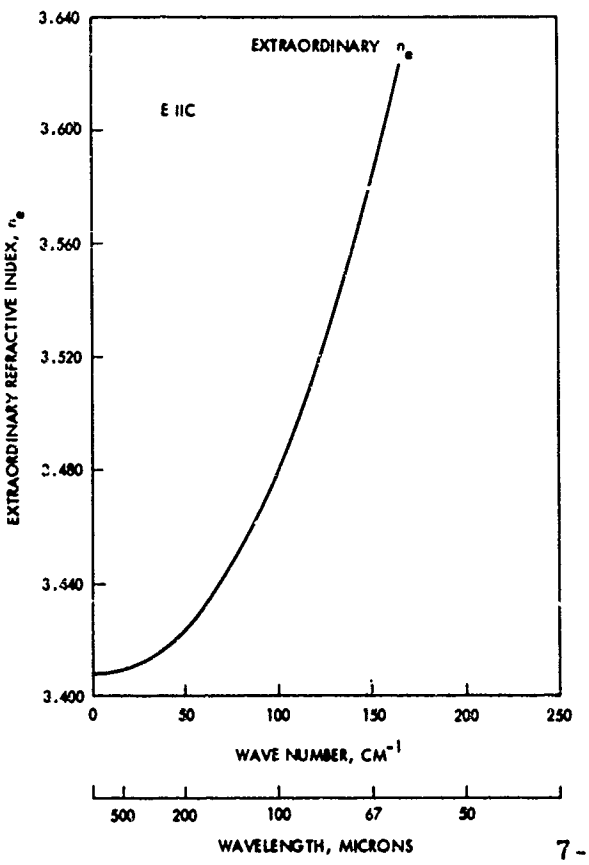



Figure 7-18

**PARAMETER:** Wavelength (Cont'd from preceding page)

**MATERIAL:** Aluminum Oxide-Sapphire

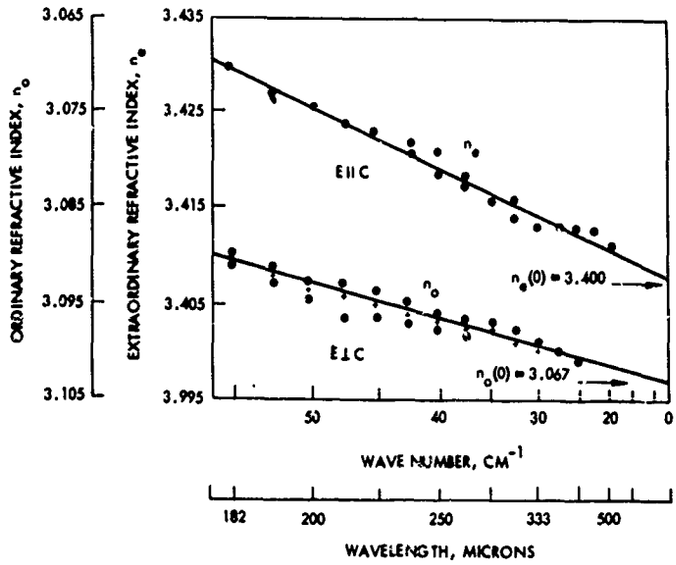



Figure 7-19

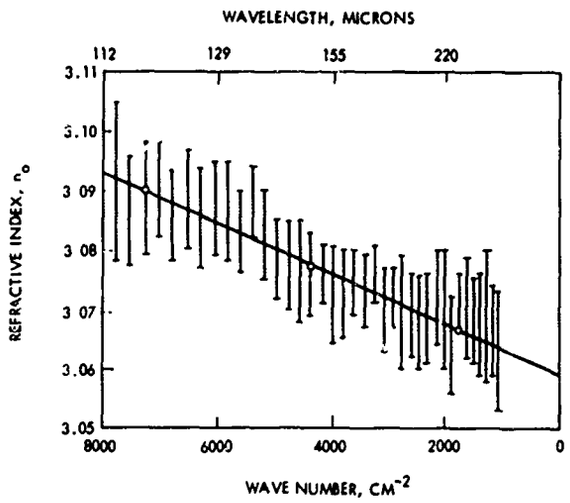
| Wave Number $cm^{-1}$ | Wavelength, (Microns) | Refractive Indices[a] | | |
|---|---|---|---|---|
| | | $n_o$ | $n_e$ | $n_e - n_o$ |
| 20.2 | | 3.0688 | 3.4111 | 0.3423 |
| 25.2 | | 3.0698 | 3.4129 | 0.3436 |
| 30.2 | 330 | 3.0704 | 3.4134 | 0.3430 |
| 35.3 | | 3.0720 | 3.4163 | 0.3443 |
| 40.3 | | 3.0740 | 3.4187 | 0.3447 |
| 45.4 | | 3.0752 | 3.4232 | 0.3480 |
| 50.4 | 200 | 3.0770 | 3.4260 | 0.3490 |
| 55.4 | | 3.0795 | 3.4294 | 0.3499 |
| 60.5 | | 3.0822 | 3.4334 | 0.3512 |
| 65.5 | | 3.0843 | 3.4391 | 0.3548 |
| 70.6 | 142 | 3.0870 | 3.4444 | 0.3574 |
| 75.6 | | 3.0906 | 3.4510 | 0.3604 |
| 80.6 | | 3.0941 | 3.4569 | 0.3628 |
| 85.7 | | 3.0982 | 3.4625 | 0.3643 |
| 90.7 | | 3.1019 | 3.4689 | 0.3670 |
| 95.8 | | 3.1060 | 3.4766 | 0.3706 |
| 100.8 | 100 | 3.1103 | 3.4836 | 0.3733 |
| 105.8 | | 3.1147 | 3.4908 | 0.3761 |
| 110.9 | | 3.1198 | 3.4993 | 0.3795 |
| 115.9 | | 3.1249 | 3.5081 | 0.3832 |
| 120.9 | 83 | 3.1304 | 3.5185 | 0.3881 |
| 126.0 | | 3.1357 | 3.5279 | 0.3922 |
| 131.0 | | 3.1422 | 3.5375 | 0.3953 |
| 136.1 | | 3.1485 | 3.5508 | 0.4023 |
| 141.1 | 71 | 3.1549 | 3.5612 | 0.4063 |
| 146.1 | | 3.1623 | 3.5746 | 0.4123 |
| 151.2 | | 3.1696 | 3.5856 | 0.4160 |
| 156.2 | 64 | 3.1765 | 3.6042 | 0.4277 |
| 161.3 | | 3.1854 | | |
| 166.3 | | 3.1921 | | |
| 171.3 | | 3.2018 | | |
| 176.4 | 57 | 3.2113 | | |

[a] The total estimated probable error of the measured values of the refractive indices is ±0.002 except at frequencies less than 25 $cm^{-1}$ and greater than 150 $cm^{-1}$ where the error may be somewhat greater.

Table 7-16

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide-Sapphire




FORM Bulk, Single Crystal

THICKNESS 1.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 112 - 300 μ

TEMPERATURE ~298 °K

METHOD Transmission

REFERENCE Roberts & Coon (18253)

REMARKS

Figure 7-20

| Wavelength, (Microns) | Refractive Index, | |
|---|---|---|
| | $n_o$ | $n_e$ |
| 167-500 | 3.14 ± 4% | 3.61 ± 4% |

THICKNESS 1.0 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 167 - 500 μ

TEMPERATURE 300 °K

METHOD Interference

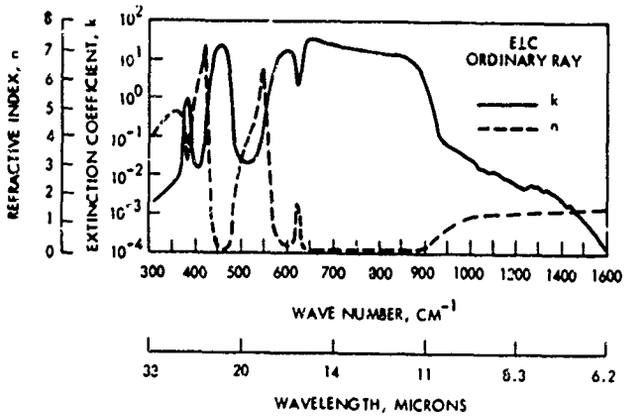
REFERENCE Loewenstein (17012)

REMARKS

Table 7-17

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide-Ruby




FORM Bulk, Single Crystal

THICKNESS 0.036 -6 (absorption, ) 5 (reflection). mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 6 - 33 μ

TEMPERATURE ~298 °K

METHOD Absorption, Reflection

REFERENCE Haefele (9762)

REMARKS Synthetic material; containing 0.04% Cr; data held valid from 0 to 0.5% Cr.

Figure 7-21

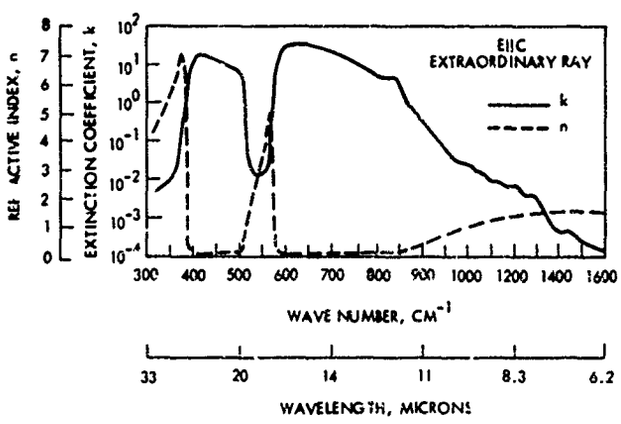



Figure 7-22

Published with permission
Copyright © 1963 Verlag der
Zeitschrift fur Naturforschung

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide, Amorphous

| Wavelength (microns) | Anodizing Potential, Volts | | |
|---|---|---|---|
| | 50 volts Refractive Index, n | 100 volts n | 200 volts n |
| 1.5 | 1.63 | 1.65 | 1.60 |
| 2 | 1.68±0.05 | 1.64±0.02 | 1.57±0.02 |
| 3 | 1.64 | 1.62 | 1.52 |
| 4 | 1.67 | 1.53 | |
| 5 | 1.63 | 1.51 | 1.49 |
| 6 | 1.66 | 1.45 | 1.43 |
| 7 | 1.67 | 1.43±01 | 1.37±0.03 |
| 8 | 1.63 | 1.42 | 1.29 |
| 9 | 1.70 | 1.40 | 1.26 |
| 10 | 1.75±0.28 | 1.51 | 1.31 |
| 11 | 1.77 | 1.55 | 1.48 |
| 12 | 1.89 | 1.73 | 1.65 |
| 13 | 2.04±0.6 | 1.86±0.4 | 1.76±0.12 |
| 14 | 2.19 | 1.94 | 1.81 |
| 15 | 2.55±0.3 | 2.04±0.3 | 1.91±0.2 |

FORM Film

THICKNESS $(0.7 - 2.8)\times10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.5 - 15 μ

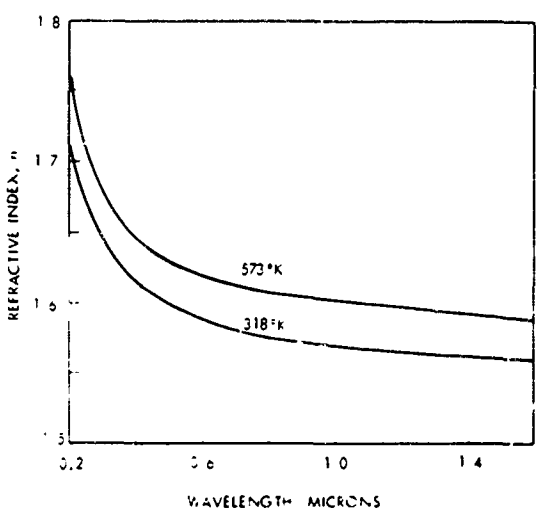
TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Harris (17011)

REMARKS Thin anodized film, removed from aluminum substrate and mounted on glass.

Table 7-18.




Published with permission
Copyright© 1964 Commission des Publications francoises de Physique

THICKNESS $(2-5)\times10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.2 - 1.6 μ

TEMPERATURE 298 °K

METHOD Reflection

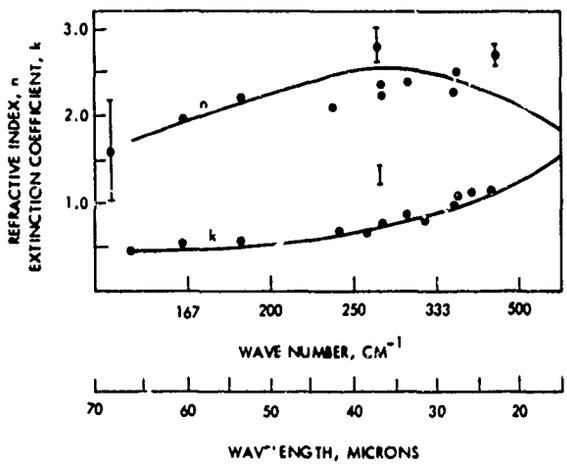
REFERENCE Cox, et al. (17066)

REMARKS Aluminum oxide produced by electron bombardment; substrate temperature as indicated.

Figure 7-23

PARAMETER: Wavelength

MATERIAL: Aluminum Oxide Amorphous




FORM Film

THICKNESS $(0.7 - 2.8) \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 15 - 67 μ

TEMPERATURE ~298 °K

METHOD Reflection, Transmission

REFERENCE Harris & Piper (5212)

REMARKS Sputtered film

Figure 7-24

PARAMETER: Temperature

MATERIAL: Aluminum Oxide Corundum

FORM Bulk, Single Crystal

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

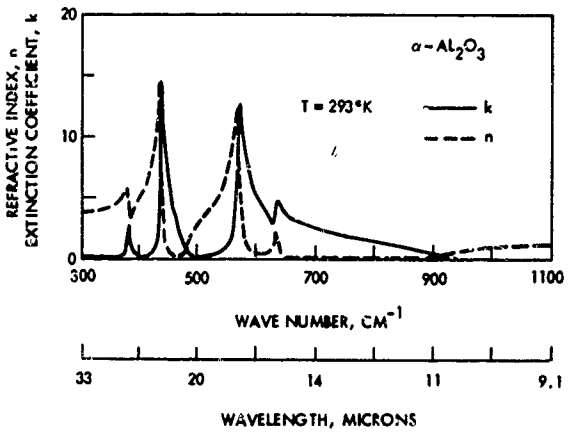
WAVELENGTH 9 - 33 μ

TEMPERATURE 293, 1773 °K

METHOD Reflection

REFERENCE Piriou (29797)

REMARKS




Published with permission
Copyright © 1966 Masson et Cie.

Figure 7-25

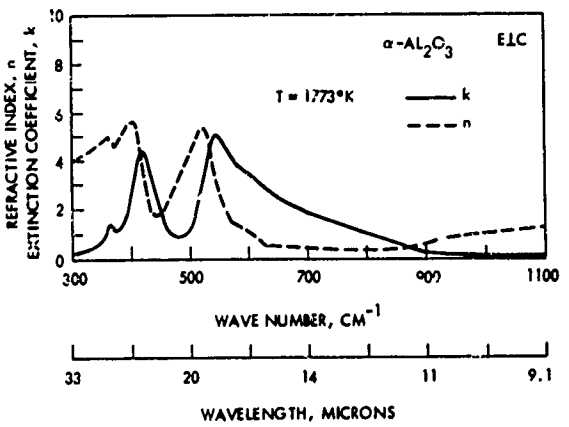



Figure 7-26

PARAMETER: Temperature

MATERIAL: Aluminum Oxide-Sapphire

"n" increases 0.05 (+0.01, -0.03) between 296 and 1973°K in the region from 0.56 to 4.0 microns.

FORM Bulk, Single Crystal

THICKNESS 1 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.56 - 4.0 μ

TEMPERATURE 296 - 1973 °K

METHOD Reflection

REFERENCE Gryvnak & Burch (21068)

REMARKS Similar results were obtained for polycrystalline material.

Table 7-19

$dn/dT = 1.0 \times 10^{-5}\ {}^{\circ}K^{-1}$

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH ~4 μ

TEMPERATURE 292, 297 °K

METHOD Deviation

REFERENCE Malitson (17008)

REMARKS

Table 7-20

## MAGNESIUM OXIDE

### INTRODUCTION

Magnesium oxide has a relatively uniform optical transmission over the range from one to six microns (Figure 1-9) and excellent high temperature characteristics. Some significant physical properties of magnesium oxide are listed in Table 1-1. Magnesium oxide is found in nature as Periclase. Magnesium oxide (magnesia) for industrial applications is often produced by precipitation of magnesium hydroxide from sea water with subsequent thermal decomposition to the oxide. Single crystals for optical use may be prepared by the submerged arc-melting process in which the unmelted material serves as its own crucible. In addition to uses of magnesium oxide in optics, the material is widely used in the manufacture of refractories, fertilizers, in the rubber industry and innumerable other applications.

### DATA

A list of data presentations on magnesium oxide is provided in Table 7-21 and temperature ranges are plotted in Figure 7-27. The wide range of temperatures from 8 to 2225°K is indicative of the environment that this material may have to endure. Refractive index and extinction coefficient data for single crystal magnesium oxide are presented as a function of wavelength in Figures 7-28 to 7-38 and Tables 7-22 and 7-23, while polycrystalline magnesium oxide is covered in Figure 7-39 and Table 7-24. The data show good agreement among various authors as well as between single and poly-crystalline material. The temperature dependence of the refractive index and extinction coefficient is the topic of Figures 7-40 to 7-46.

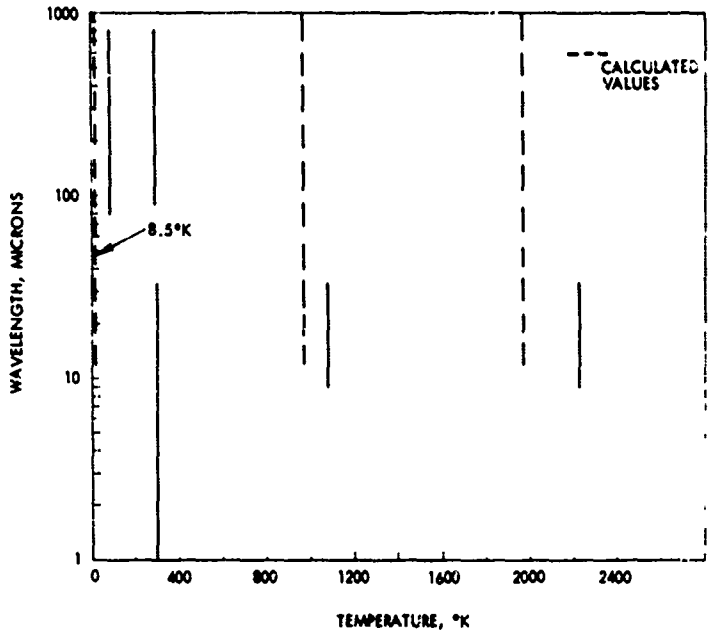


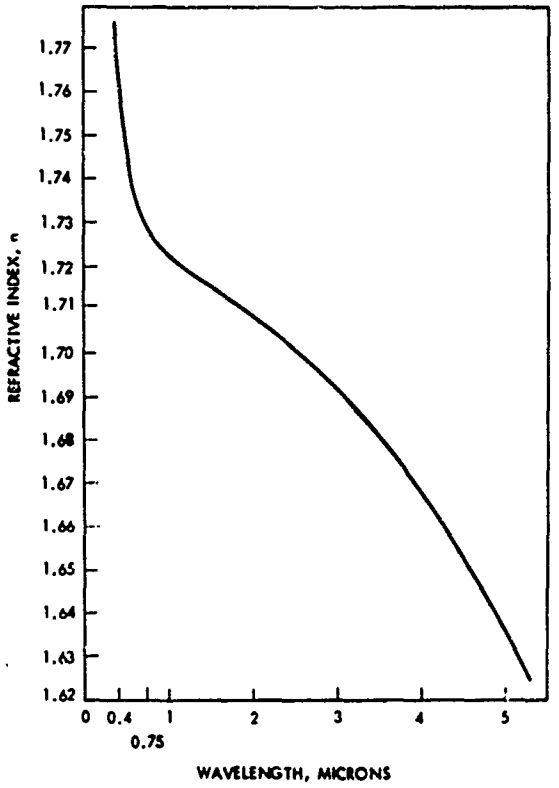

Figure 7-27. Wavelength and Temperature Range of Magnesium Oxide Data

Table 7-21

| Figure | Table | n, k | Form | Crystal | Wavelength (Microns) From | Wavelength (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|
| 7-28 | | n | Bulk | Single | 0.36 | 5.35 | | Wavelength |
| | 7-22 | n | Bulk | Single | 0.36 | 5.35 | | Wavelength |
| | 7-23 | n | Bulk | Single | 0.7 | 5.4 | | Wavelength |
| 7-29 | | n | Bulk | Single | 7.0 | 33.0 | | Wavelength |
| 7-30 | | n | Bulk | Single | 7.0 | 25.0 | | Wavelength |
| 7-31 | | k | Bulk | Single | 7.0 | 25.0 | | Wavelength |
| 7-32 | | n, k | Bulk | Single | 9.0 | 33.0 | 293°K | Wavelength |
| 7-33 | | n, k | Bulk | Single | 9.0 | 33.0 | 1080°K | Wavelength |
| 7-34 | | n, k | Bulk | Single | 9.0 | 33.0 | 2225°K | Wavelength |
| 7-35 | | n | Bulk | Single | 12.0 | 100.0 | 8-1950°K | Wavelength |
| 7-36 | | k | Bulk | Single | 12.0 | 100.0 | 8-1950°K | Wavelength |
| 7-37 | | n | Bulk | Single | 90.0 | 800.0 | 90, 300°K | Wavelength |
| 7-38 | | k | Bulk | Single | 90.0 | 800.0 | 90, 300°K | Wavelength |
| 7-39 | | n | Bulk | Polycryst | 1.0 | 9.0 | | Wavelength |
| | 7-24 | n | Bulk | Polycryst | 1.0 | 20.0 | | Wavelength |
| 7-40 | | n, k | Bulk | Single | 9.0 | 33.0 | 293°K | Temperature |
| 7-41 | | n, k | Bulk | Single | 9.0 | 33.0 | 1080°K | Temperature |
| 7-42 | | n, k | Bulk | Single | 9.0 | 33.0 | 2225°K | Temperature |
| 7-43 | | n | Bulk | Single | 12.0 | 100.0 | 8-1950°K | Temperature |
| 7-44 | | k | Bulk | Single | 12.0 | 100.0 | 8-1950°K | Temperature |
| 7-45 | | n | Bulk | Single | 90.0 | 800.0 | 90, 300°K | Temperature |
| 7-46 | | k | Bulk | Single | 90.0 | 800.0 | 90, 300°K | Temperature |

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS NA (Prism) mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.36 - 5.35 μ

TEMPERATURE 296.5 °K

METHOD Deviation

REFERENCE Stephens and Malitson (34823)

REMARKS

Figure 7-28

| Wavelength, (Microns) | Index of Refraction, n |
|---|---|
| 1.01398 | 1.72259 |
| 1.12866 | 1.72059 |
| 1.36728 | 1.71715 |
| 1.52952 | 1.71496 |
| 1.6932 | 1.71281 |
| 1.7092 | 1.71258 |
| 1.81307 | 1.71108 |
| 1.97009 | 1.70885 |
| 2.24929 | 1.70470 |
| 2.37542 | 1.70350 |
| 3.3033 | 1.68526 |
| 3.5078 | 1.66055 |
| 4.258 | 1.66039 |
| 5.138 | 1.63138 |
| 5.35 | 1.62404 |

Table 7-22

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.6907 | 1.73191 |
| 1.0140 | 1.7226 |
| 1.9701 | 1.70885 |
| 3.3033 | 1.68526 |
| 4.2580 | 1.66039 |
| 5.3500 | 1.62404 |

FORM Bulk, Single Crystal

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.7 - 5.4 μ

TEMPERATURE ~298 °K

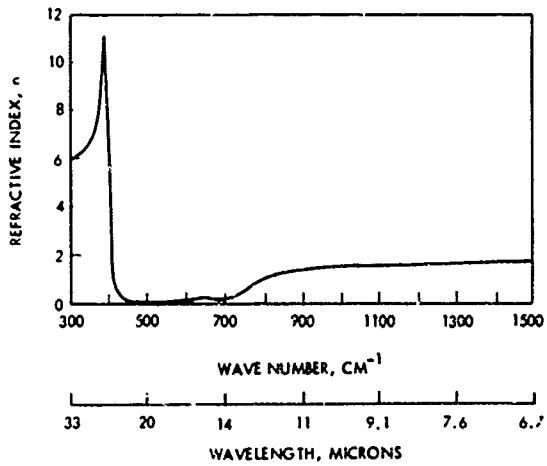
METHOD not stated

REFERENCE Norton (16227)

REMARKS Magnorite® Norton Co.

Typical analysis: 99.7 percent MgO, 0.03 percent $SiO_2$, 0.04 percent CaO, 0.05 percent $Fe_2O_3$, 0.10 percent $R_2O_3$ (other than $Fe_2O_3$).

Table 7-23




Published with permission
Copyright © 1963 Johann Ambrosius Barth

THICKNESS 0.05 - 10 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7 - 33 μ

TEMPERATURE 298 °K

METHOD Reflection

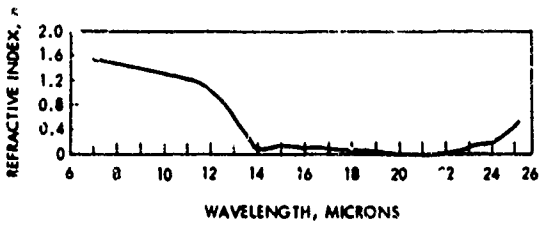
REFERENCE Haefele (34826)

REMARKS

Figure 7-29

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS 0.076 - 0.468 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 7 - 25 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Willmott (34804)

REMARKS Samples cleaved from massive crystal.

Figure 7-30

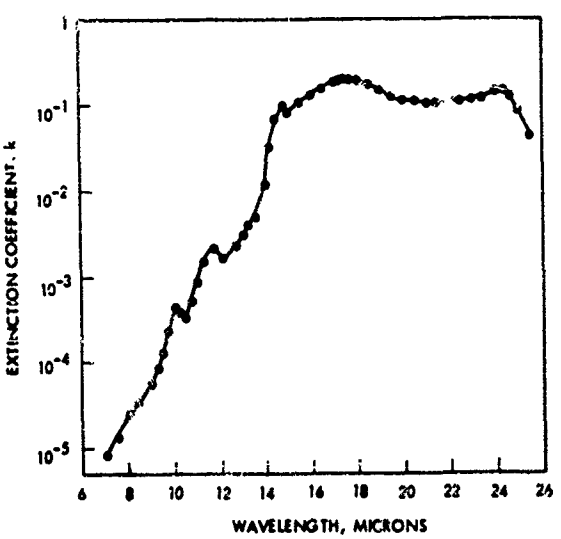
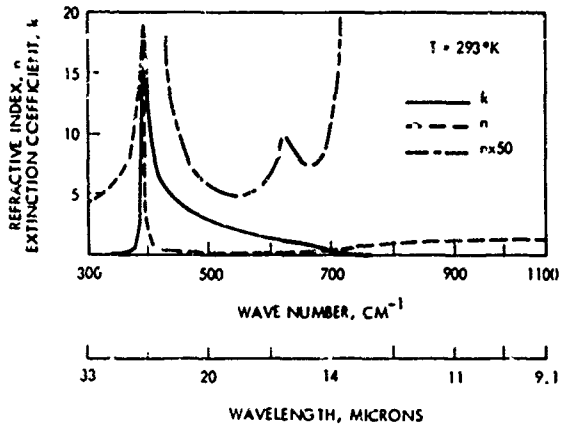



Figure 7-31

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 9 - 33 μ

TEMPERATURE 293 - 2225 °K

METHOD Reflection

REFERENCE Piriou (29797)

REMARKS

Figure 7-32

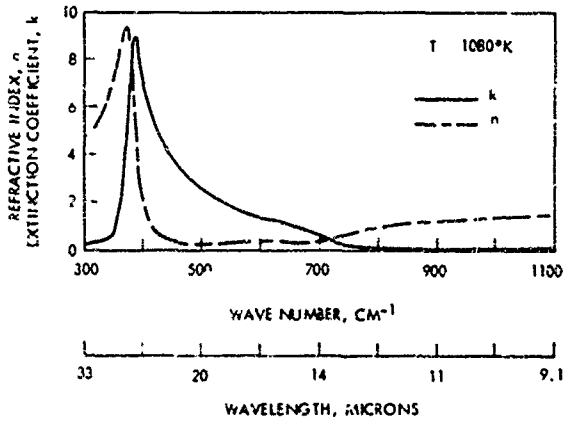



Figure 7-33

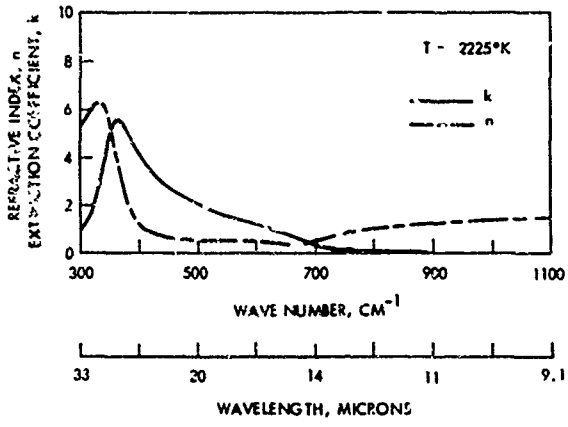
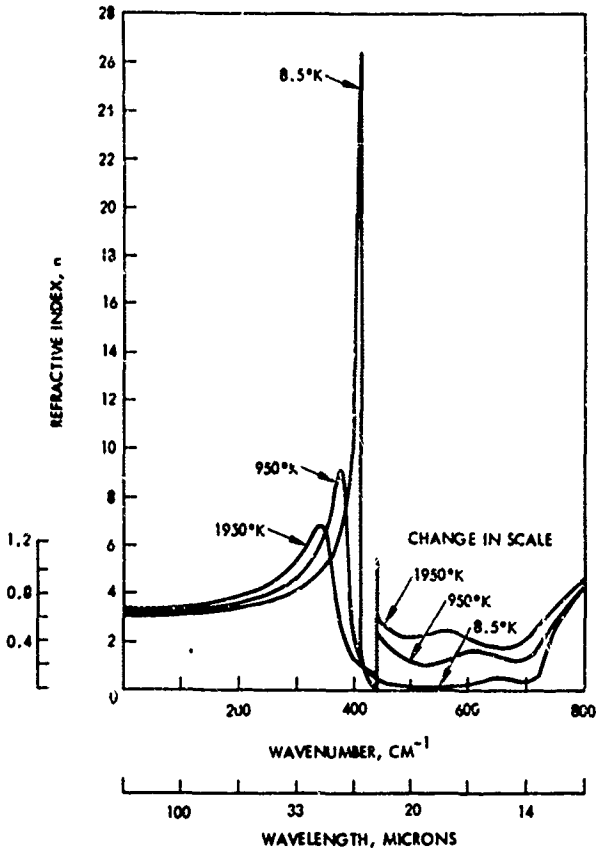



Figure 7-34

Published with permission
Copyright © 1966 Masson et Cie.

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 12 - 100 μ

TEMPERATURE 8 - 1950 °K

METHOD Reflection

REFERENCE Jasperse, et al. (34832)

REMARKS

Figure 7-35

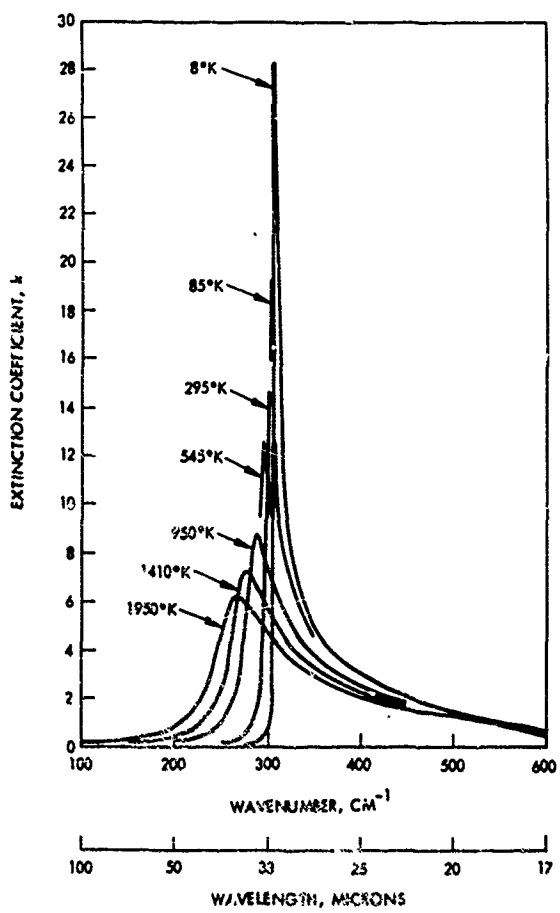



Figure 7-36

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide

FORM Bulk, Single Crystal

THICKNESS 0.436, 0.693 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 90 - 800 μ

TEMPERATURE 90, 300 °K

METHOD Transmission

REFERENCE Rowntree (34819)

REMARKS

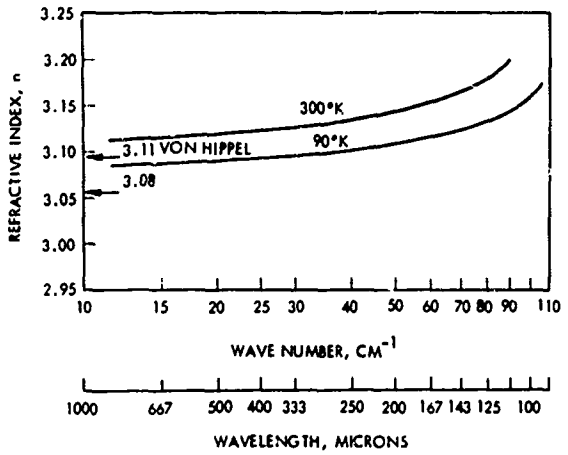



Figure 7-37

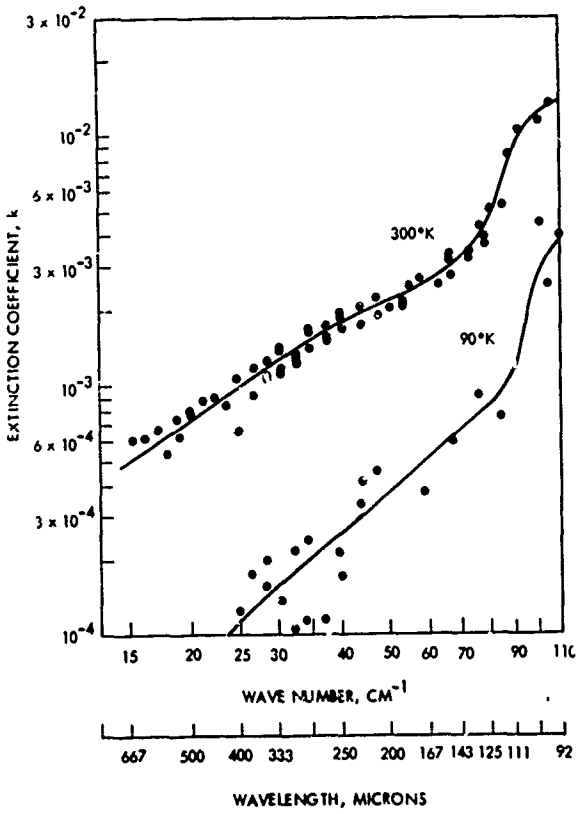
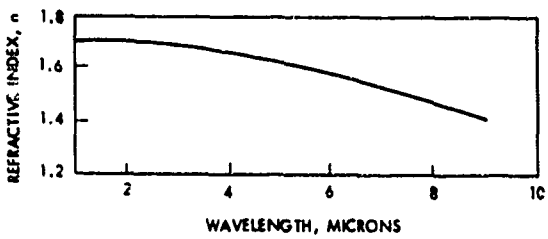



Figure 7-38

PARAMETER: Wavelength

MATERIAL: Magnesium Oxide




FORM Bulk, Polycrystalline

THICKNESS Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 20 μ

TEMPERATURE 298 °K

METHOD Not Stated

REFERENCE Kodak [1967]

REMARKS IRTRAN-5 material

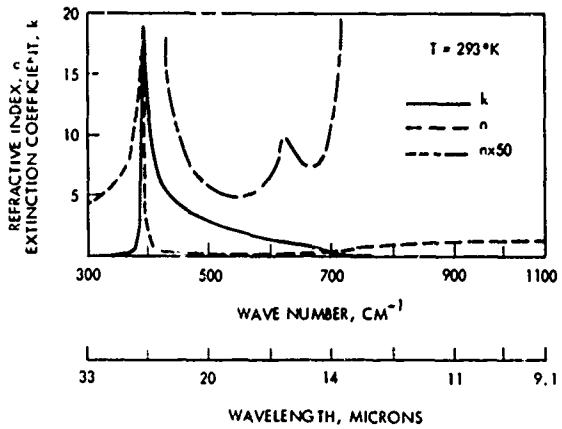
Figure 7-39

| Wavelength, (Microns) | Refractive Index, n | Wavelength, (Microns) | Refractive Index, n |
|---|---|---|---|
| 1.0000 | 1.7227 | 4.2500 | 1.6612 |
| 1.2500 | 1.7188 | 4.5000 | 1.6536 |
| 1.5000 | 1.7156 | 4.7500 | 1.6455 |
| 1.7500 | 1.7123 | 5.0000 | 1.6368 |
| 2.0000 | 1.7089 | 5.2500 | 1.6275 |
| 2.2500 | 1.7052 | 5.5000 | 1.6177 |
| 2.5000 | 1.7012 | 5.7500 | 1.6072 |
| 2.7500 | 1.6968 | 6.0000 | 1.5962 |
| 3.0000 | 1.6920 | 6.2500 | 1.5845 |
| 3.2500 | 1.6868 | 6.5000 | 1.5721 |
| 3.5000 | 1.6811 | 6.7500 | 1.5590 |
| 3.7500 | 1.6750 | 7.0000 | 1.5452 |
| 4.0000 | 1.6684 | 7.2500 | 1.5307 |
| | | 7.7500 | 1.5154 |
| | | 7.7500 | 1.4993 |
| | | 8.0000 | 1.4824 |

Table 7-24

PARAMETER: Temperature

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 9 - 33 μ

TEMPERATURE 293 - 2225 °K

METHOD Reflection

REFERENCE Piriou (29797)

REMARKS

Figure 7-40

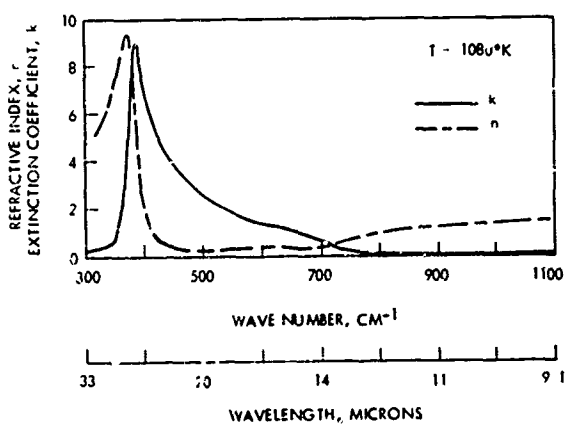



Figure 7-41

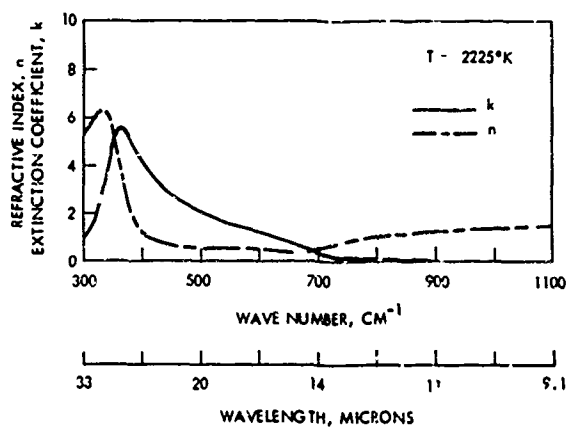
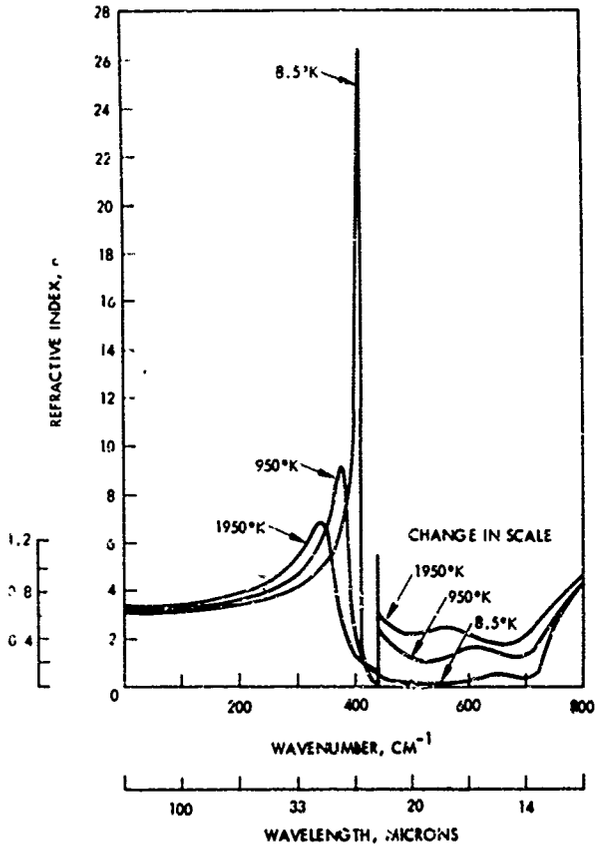



Figure 7-42

Published with permission
Copyright © 1966 Masson et Cie.

PARAMETER: Temperature

MATERIAL: Magnesium Oxide




FORM Bulk, Single Crystal

THICKNESS Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 12 - 100 μ

TEMPERATURE 8 - 1950 °K

METHOD Reflection

REFERENCE Jasperse, et al (34832)

REMARKS

Figure 7-43

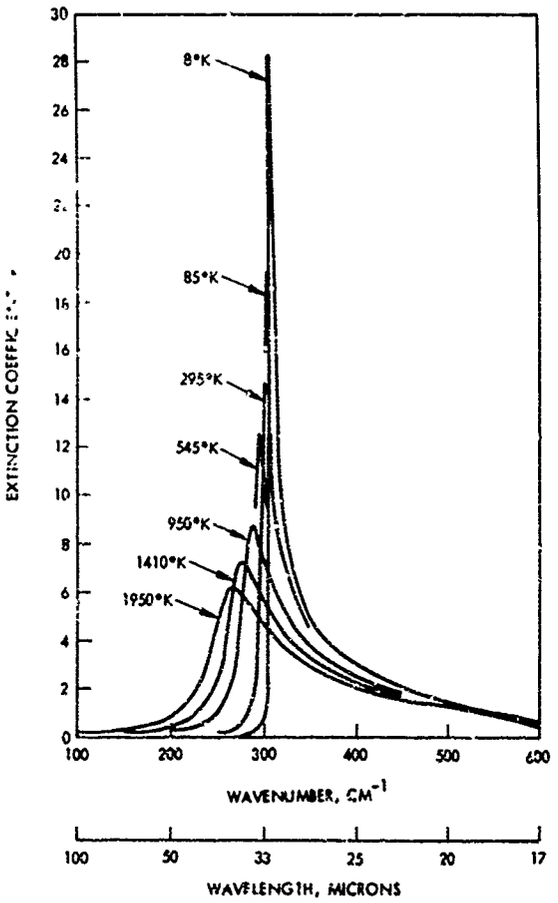
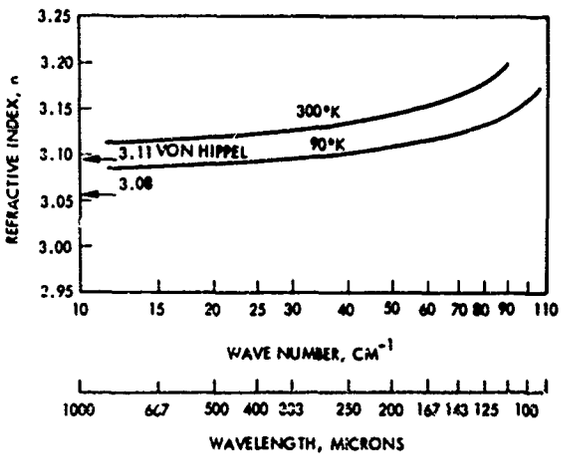



Figure 7-44

PARAMETER: Temperature

MATERIAL: Magnesium Oxide




| | |
|---|---|
| FORM | Bulk, Single Crystal |
| THICKNESS | 0.436, 0.693 mm |
| RAY | ORDINARY ☒, EXTRAORDINARY ☐ |
| WAVELENGTH | 90 - 800 μ |
| TEMPERATURE | 90, 300 °K |
| METHOD | Transmission |
| REFERENCE | Rowntree (34819) |
| REMARKS | |

Figure 7-45

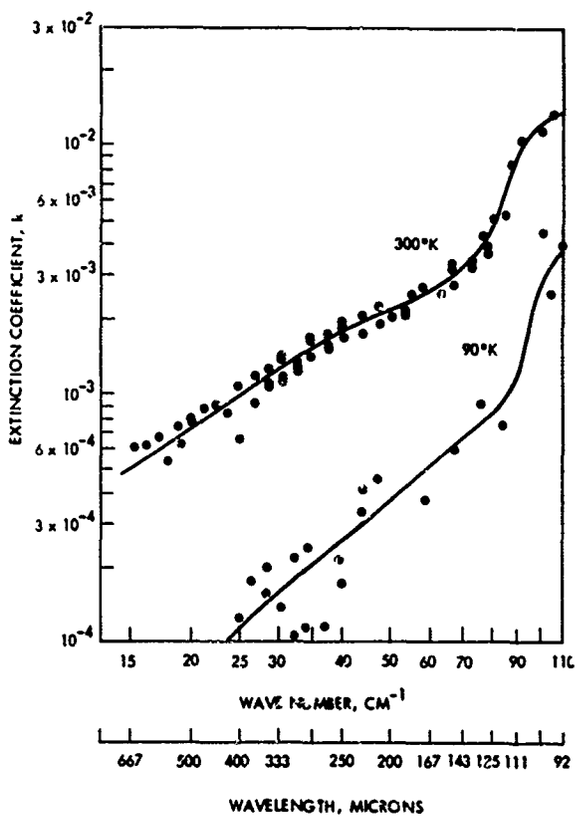



Figure 7-46

# CHAPTER 8
# REFRACTIVE INDEX DATA FOR METALS

## INTRODUCTION

This Chapter treats the optical properties of metal films comprising the metals aluminum, gold and silver. The optical behavior of metal films is dependent on film structure, and the latter is influenced by the conditions under which the film was formed. Most of the optical metal films were formed by evaporation in a vacuum of the order of $10^{-5}$ torr and, at this pressure, the residual gas atoms are sufficiently abundant to affect the film properties. Owing to the chemical inertness of gold, films of this metal should not be influenced by the presence of gases during evaporation to the same extent as aluminum and silver. In some cases a more volatile eutectic alloy may be formed between the crucible (or boat) and the metal to be evaporated, resulting in the deposition of an alloy rather than the pure metal. The crystallinity of the film is dependent on the deposition rate and substrate conditions, including type of material, orientation and temperature. Annealing conditions frequently are not detailed sufficiently to ascertain whether the film is amorphous or crystalline. The optical constants of metal films show a dependence on film thickness and often the latter either is not reported or not uniform. It should be apparent from the foregoing discussion that agreement on optical constants of metal films among various observers may be too much to hope for and, indeed, such is the case.

The data permit some generalizations which apply to all three metals. Extinction coefficients tend to show less spread among observers; this is attributed by Schulz & Tangherlini (27635) to the condition that k is dependent on the density of free electrons in the metal, and this density is probably independent of structure defects. The same authors explain the greater variation in the refractive index (n) on its dependence on the conductivity of the metal, which is highly sensitive to the presence of defects and strains.

## DATA SUMMARY

Table 8-1 lists all data presentations for aluminum, gold and silver. Figures 8-1 and Tables 8-2 to 8-8 provide aluminum data and the lowering in refractive index by an amorphous-crystalline transformation is observed (Tables 8-2 versus 8-7); data for the polycrystalline film resemble bulk data and this is not unexpected as the density of polycrystalline film approaches that of bulk material, while amorphous aluminum has a much lower density [Motulevich, et al. (25734)].

Gold data are covered in Figures 8-2 to 8-6 and Tables 8-9 to 8-20. Particularly interesting is Figure 8-3 which shows a reduction in refractive index as a result of annealing. Table 8-11 shows the great reduction which may occur in refractive index as the film thickness approaches bulk levels. Similarly, an increase in extinction coefficient is noted as the film thickness is increased (Table 8-12). Data for silver are presented in Figures 8-7 to 8-14 and Tables 8-21 to 8-31. Refractive index and extinction coefficient values have been calculated for a wide temperature range and are included as Figures 8-13 and 8-14.

## Table 8-1. List of Metal Data

| Metal | Figure | Table | n, k | Form | Crystal | Wavelength, (Microns) From | Wavelength, (Microns) To | Remarks | Parameter |
|---|---|---|---|---|---|---|---|---|---|
| Aluminum | | 8-2 | n, k | Film | Amorphous | 0.96 | 1.82 | | Wavelength |
| Aluminum | | 8-3 | n, k | | Amorphous | 2 | 12 | | Wavelength |
| Aluminum | 8-1 | | n | | * | 0.4 | 0.95 | Annealed film | Wavelength |
| Aluminum | | 8-4 | n, k | | * | 0.4 | 0.95 | Annealed film (n) | Wavelength |
| Aluminum | | 8-5 | n, k | | * | 0.8 | 9.0 | | Wavelength |
| Aluminum | | 8-6 | n | | * | 0.4 | 2.0 | | Wavelength |
| Aluminum | | 8-7 | n, k | | Polycryst | 1.0 | 1.0 | | Wavelength |
| Aluminum | | 8-8 | n, k | | * | 0.8 | 9.0 | | Temperature |
| Gold | | 8-9 | n | | Polycryst | 1 | 12 | Annealed film | Wavelength |
| Gold | | 8-10 | n, k | | * | 0.4 | 0.95 | Annealed film (n) | Wavelength |
| Gold | 8-2 | | n | | * | 0.4 | 0.95 | Annealed film | Wavelength |
| Gold | | 8-11 | n | | * | 0.8 | 1.1 | | Wavelength |
| Gold | | 8-12 | k | | * | 0.8 | 2.0 | | Wavelength |
| Gold | 8-3 | | n | | * | 0.4 | 2.5 | Annealed and unannealed film | Wavelength |
| Gold | | 8-13 | n, k | | * | 0.8 | 1.0 | | Wavelength |
| Gold | | 8-14 | n, k | | * | 0.8 | 1.0 | | Wavelength |
| Gold | | 8-15 | n, k | | * | 1.25 | 1.0 | | Wavelength |
| Gold | 8-4 | | n | | * | 1.3 | 12.1 | | Wavelength |
| Gold | | 8-16 | n | | * | 1.3 | 12.1 | | Wavelength |
| Gold | 8-5 | | n | | * | 1 | 12 | 82°K, 295°K | Wavelength |
| Gold | | 8-17 | n | | * | 1 | 11 | 82°K, 295°K | Wavelength |
| Gold | | 8-18 | n | | * | 0.8 | 1.1 | | Film Thickness |
| Gold | | 8-19 | k | | * | 0.8 | 2.0 | | Film Thickness |
| Gold | 8-6 | | n | | * | 1 | 12 | 82°K, 295°K | Temperature |
| Gold | | 8-20 | n | | * | 1 | 11 | 82°K, 295°K | Temperature |
| Silver | 8-7 | | n | | * | 0.5 | 1.5 | | Wavelength |
| Silver | | 8-21 | n, k | | * | 0.8 | 1.0 | | Wavelength |
| Silver | 8-8 | | n | | * | 0.4 | 1.0 | | Wavelength |
| Silver | 8-9 | | k | | * | 0.4 | 1.0 | | Wavelength |
| Silver | 8-10 | | n | | * | 0.4 | 0.95 | Annealed film | Wavelength |
| Silver | | 8-22 | n, k | | * | 0.4 | 0.95 | Annealed film (n) | Wavelength |
| Silver | | 8-23 | n, k | | * | 0.8 | 1.0 | | Wavelength |
| Silver | | 8-24 | n, k | | * | 1.25 | 10 | | Wavelength |
| Silver | | 8-25 | n | | * | 0.8 | 1.0 | | Wavelength |
| Silver | | 8-26 | k | | * | 0.8 | 1.5 | | Wavelength |
| Silver | 8-11 | | n | | * | 1 | 12 | 82°K, 295°K | Wavelength |
| Silver | | 8-27 | n | | * | 1 | 12 | 82°K, 295°K | Wavelength |
| Silver | 8-12 | n, k | n | | * | 0.3 | 100 | 300-1200°K | Wavelength |
| Silver | | 8-28 | n, k | | * | 1.0 | 6.0 | n-type | Wavelength |
| Silver | | 8-29 | n | | * | 0.8 | 1.0 | | Film Thickness |
| Silver | | 8-30 | k | | * | 0.8 | 1.5 | | Film Thickness |
| Silver | 8-13 | | n | | * | 1 | 12 | 82°K, 295°K | Temperature |
| Silver | | 8-31 | n | | * | 1 | 12 | 82°K, 295°K | Temperature |
| Silver | 8-14 | | n, k | | * | 0.3 | 100 | 300-1200°K | Temperature |

*Not stated.

PARAMETER: Wavelength

MATERIAL: Aluminum

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.96 | 2.0 | 10.2 |
| 1.15 | 1.8 | 12.0 |
| 1.46 | 3.1 | 16.4 |
| 1.82 | 4.9 | 19.9 |

FORM Film-Amorphous

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.96-1.82 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Motulevich, et al. (25734)

REMARKS Film deposited on glass, resulting in sample of mean density of 2.2 g·cm$^{-3}$

Table 8-2

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 2.0 | 2.30 | 16.5 |
| 2.5 | 3.22 | 20.3 |
| 3.0 | 4.41 | 24.2 |
| 4.0 | 5.97 | 30.3 |
| 5.0 | 8.19 | 36.8 |
| 6.0 | 11.00 | 42.4 |
| 7.0 | 14.63 | 49.0 |
| 8.0 | 17.00 | 55.0 |
| 9.0 | 21.1 | 61.3 |
| 10.0 | 25.4 | 67.3 |
| 11.0 | 28.3 | 71.1 |
| 12.0 | 33.6 | 76.4 |

THICKNESS $1.5 \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 2 - 12 μ

TEMPERATURE 298 °K

METHOD Reflection

REFERENCE Beattie [1955]

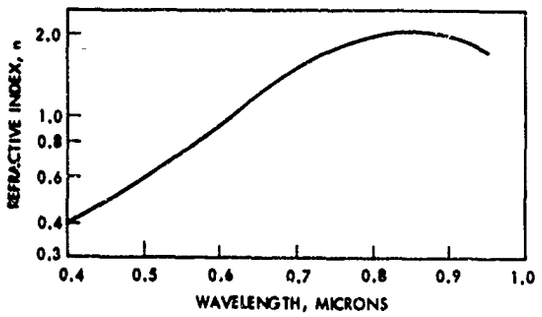
REMARKS Specimens evaporated onto glass substrate at ~ $10^{-5}$ torr pressure.

Table 8-3

PRECEDING PAGE BLANK

PARAMETER: Wavelength

MATERIAL: Aluminum




FORM Film

THICKNESS $1.5 \times 10^{-4}$ (n); $5 \times 10^{-5}$ (k) mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 0.4 - 0.95 μ

TEMPERATURE ~298 °K

METHOD Reflection (n); Interference (k).

REFERENCE Schulz Tangherlin (27635) for n; Schulz (27634) for k.

REMARKS Evaporation from tungsten wire at $10^{-5}$ Torr onto glass substrate for n and mica substrate for k.

Figure 8-1

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.40 | 0.40 | 3.92 |
| 0.45 | 0.49 | 4.32 |
| 0.50 | 0.62 | 4.80 |
| 0.55 | 0.76 | 5.32 |
| 0.60 | 0.97 | 6.00 |
| 0.65 | 1.24 | 6.60 |
| 0.70 | 1.55 | 7.00 |
| 0.75 | 1.80 | 7.12 |
| 0.80 | 1.99 | 7.05 |
| 0.85 | 2.08 | 7.15 |
| 0.90 | 1.96 | 7.70 |
| 0.95 | 1.75 | 8.50 |

Table 8-4

PARAMETER: Wavelength

MATERIAL: Aluminum

| Wavelength, (Microns) | Refractive Index, n | | Extinction Coefficient, k | |
|---|---|---|---|---|
| | 78°K | 295°K | 78°K | 295°K |
| 0.8 | 0.83 | 1.12 | 6.0 | 6.0 |
| 0.9 | 0.75 | 1.05 | 7.0 | 7.0 |
| 1.2 | 0.63 | 0.95 | 9.6 | 9.6 |
| 1.5 | 0.78 | 1.14 | 12.1 | 12.1 |
| 2.0 | 1.30 | 1.75 | 16.1 | 16.1 |
| 2.5 | 1.7 | 2.4 | 19.8 | 19.8 |
| 3.0 | 2.2 | 3.2 | 23.5 | 23.5 |
| 4.0 | 3.2 | 4.8 | 30.1 | 30.0 |
| 5.0 | 4.4 | 6.7 | 37.8 | 37.6 |
| 6.0 | 6.5 | 9.5 | 44.9 | 44.4 |
| 7.0 | | 12.6 | 52.0 | 49.0 |
| 8.0 | | 15.6 | | 55.0 |
| 9.0 | | 21.1 | | 61.3 |

FORM Film

THICKNESS $1.5 \times 10^{-5}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 9.0 μ

TEMPERATURE 78, 295 °K

METHOD Reflection

REFERENCE Golovashkin, et al. (14298)

REMARKS Film formed by vacuum evaporation from tungsten helix onto glass.

Table 8-5

| Wavelength, (Microns) | Refractive Index, n |
|---|---|
| 0.40 | 0.32 |
| 0.70 | 1.26 |
| 0.75 | 1.50 |
| 0.80 | 1.78 |
| 0.85 | 1.91 |
| 0.875 | 1.82 |
| 0.90 | 1.70 |
| 0.95 | 1.40 |
| 1.00 | 1.17 |
| 1.10 | 0.85 |
| 1.20 | 0.78 |
| 1.50 | 1.00 |
| 1.70 | 1.31 |
| 2.00 | 1.74 |

THICKNESS. Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.40 - 2.00 μ

TEMPERATURE 298 °K

METHOD Reflection

REFERENCE Shlkyarevskii and Yarovaya (19998)

REMARKS Evaporation at $2 \times 10^{-5}$ torr onto glass substrate

Table 8-6

PARAMETER: Wavelength

MATERIAL: Aluminum

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 1.00 | 0.98 | 7.65 |
| 1.50 | 1.14 | 11.6 |
| 2.00 | 1.67 | 15.2 |
| 2.50 | 2.50 | 18.8 |
| 3.00 | 3.48 | 22.6 |
| 4.00 | 5.58 | 29.4 |
| 5.00 | 7.84 | 35.7 |
| 6.00 | 10.4 | 41.3 |
| 8.00 | 16.2 | 52.2 |
| 10.0 | 25.5 | 60.9 |

FORM Film - Polycrystalline

THICKNESS Not Stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 10 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Motulevich, et al. (25734)

REMARKS Film deposited on glass, resulting in sample density of 2.7 g $cm^{-3}$.

Table 8-7

PARAMETER: Temperature

MATERIAL: Aluminum

| Wavelength, Microns | Refractive Index, n | | Extinction Coefficient, k | |
|---|---|---|---|---|
| | 78°K | 295°K | 78°K | 295°K |
| 0.8 | 0.83 | 1.12 | 6.0 | 6.0 |
| 0.9 | 0.75 | 1.05 | 7.0 | 7.0 |
| 1.2 | 0.63 | 0.95 | 9.6 | 9.6 |
| 1.5 | 0.78 | 0.14 | 12.1 | 12.1 |
| 2.0 | 1.30 | 1.75 | 16.1 | 16.1 |
| 2.5 | 1.7 | 2.4 | 19.8 | 19.8 |
| 3.0 | 2.2 | 3.2 | 23.5 | 23.5 |
| 4.0 | 3.2 | 4.8 | 30.1 | 30.0 |
| 5.0 | 4.4 | 6.7 | 37.8 | 37.6 |
| 6.0 | 6.5 | 9.5 | 44.9 | 44.4 |
| 7.0 | | 12.6 | 52.0 | 49.0 |
| 8.0 | | 15.6 | | 55.0 |
| 9.0 | | 21.1 | | 61.3 |

FORM Film

THICKNESS $1.5 \times 10^{-5}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 9.0 μ

TEMPERATURE 78, 295 °K

METHOD Reflection

REFERENCE Golovashkin, et al. (14298)

REMARKS Film formed by vacuum evaporation from tungsten helix onto glass.

Table 8-8

PARAMETER: Wavelength

MATERIAL: Gold

| Wavelength, Microns | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 1.0 | 0.224 | 6.71 |
| 1.5 | 0.357 | 10.4 |
| 2.0 | 0.546 | 13.9 |
| 2.5 | 0.82 | 17.3 |
| 3.0 | 1.17 | 21.0 |
| 4.0 | 2.04 | 27.9 |
| 5.0 | 3.27 | 35.2 |
| 6.0 | 4.70 | 41.7 |
| 8.0 | 7.82 | 54.6 |
| 10.0 | 11.5 | 67.5 |
| 12.0 | 15.4 | 80.5 |

FORM Film - Polycrystalline

THICKNESS $(0.5 - 1) \times 10^{-3}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 12 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Motulevich & Shubin (19922)

REMARKS Evaporation at $3 \times 10^{-6}$ torr pressure from tungsten onto glass substrate, followed by anneal of at least three hours at $10^{-6}$ torr and 673°K.

Table 8-9

PRECEDING PAGE BLANK

PARAMETER: Wavelength

MATERIAL: Gold

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.40 | 1.45 | |
| 0.45 | 1.40 | 1.88 |
| 0.50 | 0.84 | 1.84 |
| 0.55 | 0.34 | 2.37 |
| 0.60 | 0.23 | 2.97 |
| 0.65 | 0.19 | 3.50 |
| 0.70 | 0.17 | 3.97 |
| 0.75 | 0.16 | 4.42 |
| 0.80 | 0.16 | 4.84 |
| 0.85 | 0.17 | 5.30 |
| 0.90 | 0.18 | 5.72 |
| 0.95 | 0.19 | 6.10 |

FORM Film

THICKNESS $(1.5-2) \times 10^{-4}$ mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.4 - 0.95 μ

TEMPERATURE ~298 °K

METHOD Reflection (n); Interference (k).

REFERENCE Schulz & Tangherline (27635) for n, Schulz (27634) for k.

REMARKS Evaporation from tungsten wire at $10^{-5}$ torr onto glass substrate for n and mica substrate for k. Glass substrate sample annealed at <403° K

Table 8-10

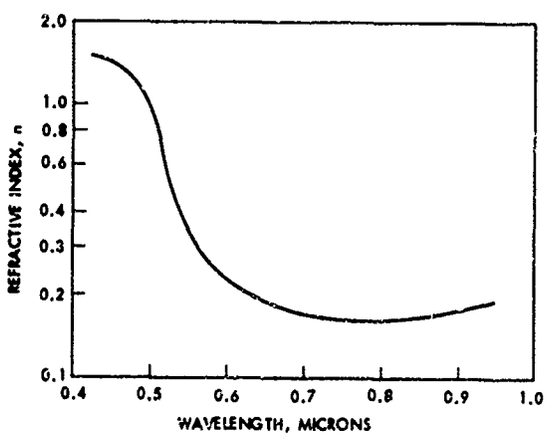



Figure 8-2

PARAMETER: Wavelength

MATERIAL: Gold

FORM Film

THICKNESS $1 \times 10^{-6}$ to bulk mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.1 μ

TEMPERATURE ~298 °K

METHOD Miscellaneous

REFERENCE Mayer [1950]

REMARKS Compilation of older data

| Film Thickness, Å | Refractive Index, n @ Wavelength Microns | | | | Observer |
|---|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | 1.1 | |
| 10 | 4.35 | 4.5 | 4.85 | 5.05 | Goos [1937] |
| 20 | 5.25 | 5.1 | 5.0 | 5.0 | Goos [1937] |
| 30 | 5.05 | 5.15 | 5.0 | 5.0 | Goos [1937] |
| 40 | 4.15 | 4.7 | 4.9 | 5.15 | Goos [1937] |
| 50 | 4.3 | 4.55 | 4.9 | 5.15 | Goos [1937] |
| 75 | 4.3 | 4.6 | 4.75 | 5.15 | Goos [1937] |
| 100 | 3.5 | 3.95 | 4.35 | 4.85 | Goos [1937] |
| 150 | 1.4 | 1.8 | 2.15 | 2.55* | Goos [1937] |
| 200 | 0.45 | 0.5 | 0.55 | 0.6 | Goos [1937] |
| 400 | 0.18 | 0.19 | 0.195 | | Kretzmann (40353) |
| ∞ | 0.2 | 0.25 | 0.25 | 0.3 | Pogany [1916] |

*Thickness range 100-400 Å

Table 8-11

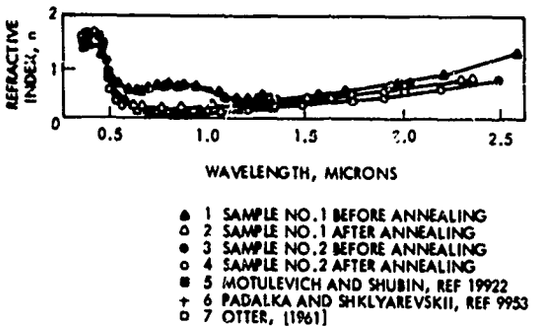
| Film Thickness, Å | Extinction Coefficient, k @ Wavelength Microns | | | | | | Observer |
|---|---|---|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | 1.1 | 1.5 | 2.0 | |
| 10 | 0.7 | 0.5 | 0.25 | 0.05 | | | Goos [1937] |
| 20 | 1.65 | 1.1 | 0.7 | 0.35 | | | Goos [1937] |
| 30 | 2.75 | 1.75 | 1.25 | 0.8 | | | Goos [1937] |
| 40 | 2.9 | 2.3 | 1.95 | 1.3 | | | Goos [1937] |
| 50 | 3.3 | 2.8 | 2.6 | 2.0 | | | Goos [1937] |
| 75 | 4.1 | 3.75 | 3.6 | 5.3 | | | Goos [1937] |
| 100 | 4.55 | 4.5 | 4.4 | 4.4 | | | Goos [1937] |
| | 5.56* | | | | | | Haringhuizen, et al. [1937] |
| 150 | 5.0 | 5.45 | 5.8 | 6.4 | | | Goos [1937] |
| 200 | 5.2 | 5.9 | 6.7 | 7.5 | | | Goos [1937] |
| 500-1000 | 5.19 | | 6.9 | | 11.3 | 15.4 | Hagen & Rubens [1902] |
| ∞ | 5.2 | 6.0 | 6.95 | 7.65 | | | Goos [1937] |
| | 4.2 | 4.93 | 5.57 | | | | Statescu [1910] |

*Thickness range 100-400 Å

Table 8-12

PARAMETER: Wavelength

MATERIAL: Gold




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.4 - 2.5 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Shklyarevskii & Yarovaya (27261)

REMARKS Deposition rates: Sample No. 1- one Å $sec^{-1}$, sample No. 2- 100 Å $sec^{-1}$. Samples annealed at 393° K in vacuo after deposition, where stated.

Figure 8-3

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.800 | 0.178 | 4.20 |
| 0.850 | 0.182 | 4.53 |
| 0.900 | 0.190 | 4.93 |
| 0.950 | 0.199 | 5.27 |
| 1.000 | 0.194 | 5.57 |

THICKNESS 0.33 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.80 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Kretzmann (40353)

REMARKS Evaporation from tungsten or molybdenum crucibles at $<1 \times 10^{-4}$ torr.

Table 8-13

PARAMETER: Wavelength

MATERIAL: Gold

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.800 | 0.149 | 4.654 |
| 0.850 | 0.157 | 4.993 |
| 0.900 | 0.166 | 5.335 |
| 0.950 | 0.174 | 5.691 |
| 1.000 | 0.179 | 6.044 |

FORM Film

THICKNESS 0.3 - 0.4 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Weiss (6107)

REMARKS Evaporation onto silica substrate at $2 \times 10^{-5}$ torr pressure

Table 8-14

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 1.25 | 0.38 | 8.0 |
| 1.5 | 0.53 | 9.5 |
| 2 | 0.85 | 12.6 |
| 3 | 1.64 | 18.6 |
| 4 | 2.6 | 24.6 |
| 5 | 3.8 | 30.7 |
| 6 | 5.1 | 36.4 |
| 7 | 6.8 | 41.6 |
| 8 | 8.5 | 46.4 |
| 9 | 10.5 | 50.8 |
| 10 | 12.4 | 55.0 |

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.25 - 10 μ

TEMPERATURE 293 °K

METHOD Reflection

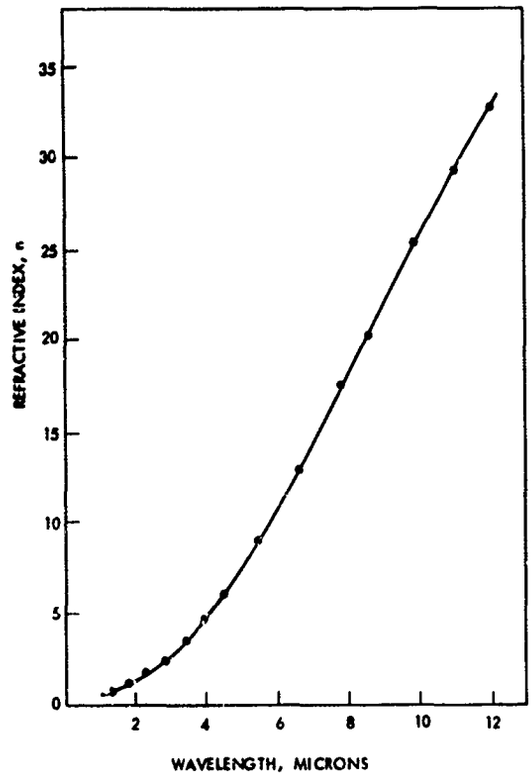
REFERENCE Dold & Mecke (27079)

REMARKS Evaporation from tantalum crucible.

Table 8-15

PARAMETER: Wavelength

MATERIAL: Gold




FORM Film

THICKNESS $(1.5 - 2) \times 10^{-3}$ mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 1 - 12 $\mu$

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Shkliarevskii & Padalka (36056)

REMARKS Vacuum evaporation from molybdenum crucible onto glass substrate. According to the authors, samples may have been insufficiently clean, resulting in high refractive indices.

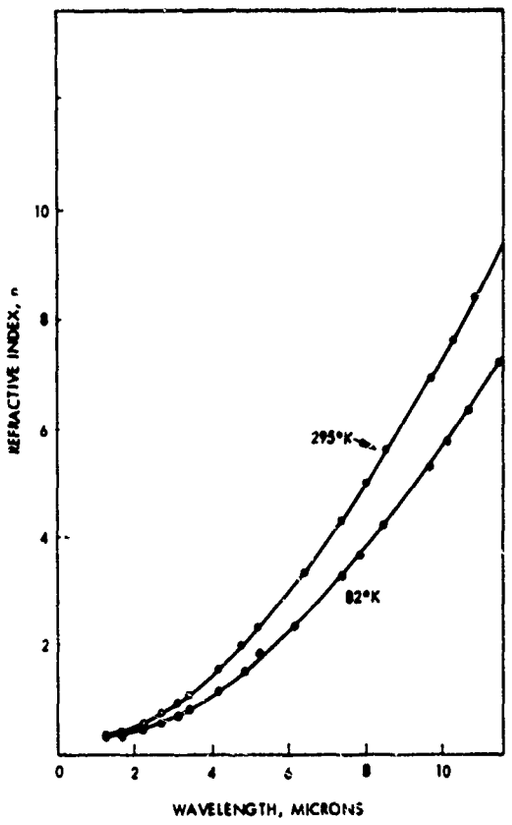
Figure 8-4

| Wavelength (Microns) | Refractive Index, n |
|---|---|
| 1.3 | 0.69 |
| 1.75 | 1.1 |
| 1.95 | 1.3 |
| 2.26 | 1.62 |
| 2.8 | 2.2 |
| 3.43 | 3.49 |
| 3.95 | 4.71 |
| 4.55 | 5.95 |
| 5.5 | 9.05 |
| 6.65 | 12.9 |
| 7.9 | 17.6 |
| 8.65 | 20.2 |
| 9.9 | 25.2 |
| 11.1 | 29.0 |
| 12.1 | 32.4 |

Table 8-16

PARAMETER: Wavelength

MATERIAL: Gold




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 12 μ

TEMPERATURE 82, 295 °K

METHOD Reflection

REFERENCE Padalka & Shklyarevskii (9953)

REMARKS Evaporation from tantalum crucible onto glass substrate at $\sim 10^{-5}$ torr pressure.

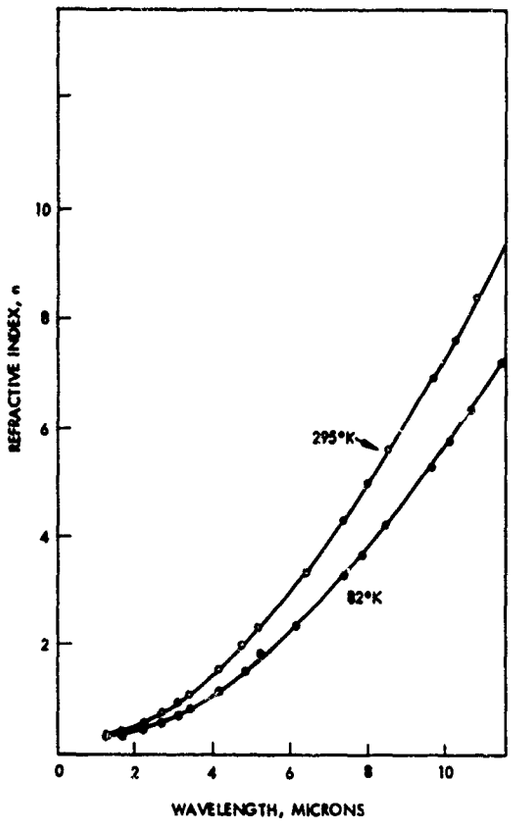
Figure 8-5

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | T = 295°K | T = 82°K |
| λ (μ) | n | n |
| 1 | 0.31 | 0.28 |
| 2 | 0.54 | 0.45 |
| 3 | 0.93 | 0.74 |
| 4 | 1.49 | 1.15 |
| 5 | 2.19 | 1.67 |
| 6 | 3.01 | 2.29 |
| 7 | 3.97 | 2.99 |
| 8 | 5.05 | 3.84 |
| 9 | 6.21 | 4.74 |
| 10 | 7.41 | 5.70 |
| 11 | 8.71 | 6.76 |

Table 8-17

**PARAMETER:** Temperature

**MATERIAL:** Gold




**FORM** Film

**THICKNESS** Not stated mm

**RAY** ORDINARY ☒ , EXTRAORDINARY ☐

**WAVELENGTH** 1 - 12 μ

**TEMPERATURE** 82, 295 °K

**METHOD** Reflection

**REFERENCE** Padalka & Shklyarevskii (9953)

**REMARKS** Evaporation from tantalum crucible onto glass substrate at $10^{-5}$ torr pressure.

Figure 8-6

**PARAMETER:** Film Thickness

**MATERIAL:** Gold

**FORM** Film

**THICKNESS** $1 \times 10^{-6}$ to bulk mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.8 - 1.1 μ

**TEMPERATURE** ~298 °K

**METHOD** Miscellaneous

**REFERENCE** Mayer [1950]

**REMARKS** Compilation of older data

| Film Thickness Å | Refractive Index, n @ Wavelength, Microns 0.8 | 0.9 | 1.0 | 1.1 | Observer |
|---|---|---|---|---|---|
| 10 | 4.35 | 4.5 | 4.95 | 5.05 | Goos [1937] |
| 20 | 5.25 | 5.1 | 5.0 | 5.0 | Goos [1937] |
| 30 | 5.05 | 5.15 | 5.0 | 5.0 | Goos [1937] |
| 40 | 4.15 | 4.7 | 4.9 | 5.15 | Goos [1937] |
| 50 | 4.3 | 4.55 | 4.9 | 5.15 | Goos [1937] |
| 75 | 4.3 | 4.6 | 4.75 | 5.15 | Goos [1937] |
| 100 | 3.5 | 3.95 | 4.35 | 4.85 | Goos [1937] |
| 150 | 1.4 | 1.8 | 2.15 | 2.55* | Goos [1937] |
| 200 | 0.45 | 0.5 | 0.55 | 0.6 | Goos [1937] |
| 400 | 0.18 | 0.19 | 0.195 | | Kretzmann (40353) |
| ∞ | 0.2 | 0.25 | 0.25 | 0.3 | Pogany [1916] |

*Thickness range 100-400 A

Table 8-18

| Film Thickness, Å | Extinction Coefficient, k @ Wavelength, Microns 0.8 | 0.9 | 1.0 | 1.1 | 1.5 | 2.0 | Observer |
|---|---|---|---|---|---|---|---|
| 10 | 0.7 | 0.5 | 0.25 | 0.35 | | | Goos [1937] |
| 20 | 1.45 | 1.1 | 0.7 | 0.35 | | | Goos [1937] |
| 30 | 2.75 | 1.75 | 1.25 | 0.8 | | | Goos [1937] |
| 40 | 2.9 | 2.3 | 1.95 | 1.3 | | | Goos [1937] |
| 50 | 3.3 | 2.8 | 2.6 | 2.0 | | | Goos [1937] |
| [illegible] | 4.1 | 3.75 | 3.[illegible] | 5.3 | | | Goos [1937] |
| 100 | 4.55 | 4.5 | 4.4 | 4.4 | | | Goos [1937] |
| | 5.5* | | | | — | | Haringhuizen, et al. [1937] |
| 1[illegible] | 5.0 | 5.45 | 5.8 | 6.4 | | | Goos [1937] |
| 200 | 5.2 | 5.9 | 6.7 | 7.5 | — | | Goos [1937] |
| [illegible] | 5.19 | | [illegible] | | 11.3 | 15.4 | Hagen & Rubens [1902] |
| ∞ | 5.2 | 5.0 | [illegible] | 7.65 | | | Goos [1937] |
| | 4.2 | 4.[illegible] | 5.57 | | | | Statescu [1910] |

*Thickness range 100-400 Å

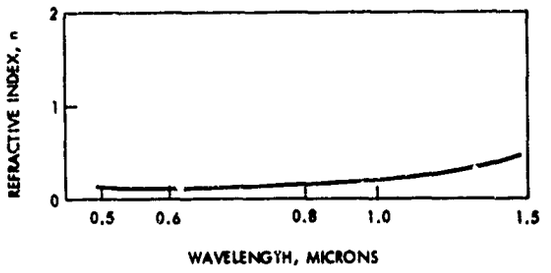
Table 8-19

TABLE 8-20

Not included in this report.
We will not receive this table.
M. Anderson
DDC-TCA
13 May 70

PARAMETER: Wavelength

MATERIAL: Silver




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒ EXTRAORDINARY ☐

WAVELENGTH 0.5 - 1.5 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Yarovaya & Shklyarevskii (36165)

REMARKS Samples identical to Ref. 9953.

Figure 8-7

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.800 | 0.196 | 5.54 |
| 0.850 | 0.200 | 5.87 |
| 0.900 | 0.227 | 6.26 |
| 0.950 | 0.245 | 6.61 |
| 1.000 | 0.263 | 6.93 |

THICKNESS 0.17 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Kretzmann (40353)

REMARKS Evaporation from tungsten or molybdenum crucible at $<1 \times 10^{-4}$ torr pressure.

Table 8-21

**PARAMETER:** Wavelength

**MATERIAL:** Silver

**FORM** Film

**THICKNESS** $>0.7 \times 10^{-4}$ mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.4 - 1.0 μ

**TEMPERATURE** ~298 °K

**METHOD** Reflection, Transmission

**REFERENCE** Idczak [1967]

**REMARKS** Film prepared by evaporation onto glass substrate at $\sim 10^{-4}$ torr.

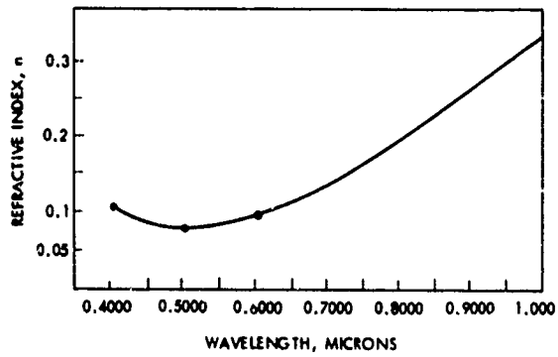



Figure 8-8

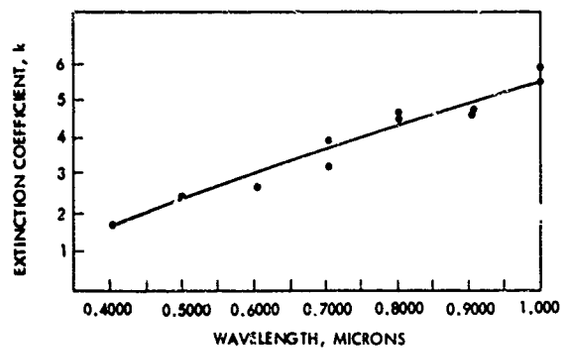



Figure 8-9

PARAMETER: Wavelength

MATERIAL: Silver

FORM Film

THICKNESS $1.5 \times 10^{-4}$ for n, $5 \times 10^{-5}$ for k mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.4 - 0.95 μ

TEMPERATURE ~298 °K

METHOD Reflection (n); Interference (k)

REFERENCE Schulz & Tangherlini (27635) for n, Schulz (27634) for k.

REMARKS Evaporation from molybdenum crucible at $\sim 10^{-5}$ torr onto glass substrate for n, mica substrate for k.

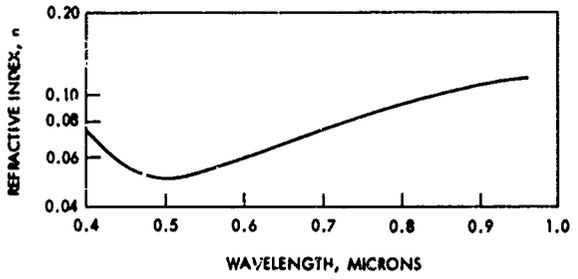



Figure 8-10

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.40 | 0.075 | 1.93 |
| 0.45 | 0.055 | 2.42 |
| 0.50 | 0.050 | 2.87 |
| 0.55 | 0.055 | 3.32 |
| 0.60 | 0.060 | 3.75 |
| 0.65 | 0.070 | 4.20 |
| 0.70 | 0.075 | 4.62 |
| 0.75 | 0.080 | 5.05 |
| 0.80 | 0.090 | 5.45 |
| 0.85 | 0.100 | 5.85 |
| 0.90 | 0.105 | 6.22 |
| 0.95 | 0.110 | 6.56 |

Table 8-22

PARAMETER: Wavelength

MATERIAL: Silver

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 0.800 | 0.110 | 5.409 |
| 0.850 | 0.121 | 5.757 |
| 0.900 | 0.128 | 6.089 |
| 0.950 | 0.130 | 6.476 |
| 1.000 | 0.129 | 6.829 |

FORM Film

THICKNESS 0.12 - 0.20 mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.00 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Weiss (6107)

REMARKS Evaporation from tungsten or molybdenum crucible onto silica substrate at $2 \times 10^{-5}$ torr.

Table 8-23

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 1.25 | 0.37 | 7.7 |
| 1.5 | 0.45 | 9.0 |
| 2 | 0.65 | 12.2 |
| 3 | 1.30 | 18.2 |
| 4 | 2.3 | 24.3 |
| 5 | 3.5 | 30.4 |
| 6 | 5.0 | 36.0 |
| 7 | 6.9 | 41.0 |
| 8 | 8.9 | 46.0 |
| 9 | 11.0 | 50.0 |
| 10 | 13.3 | 54.0 |

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1.25 - 10 μ

TEMPERATURE 293 °K

METHOD Reflection

REFERENCE Dold & Mecke (27079)

REMARKS Evaporation from molybdenum crucible.

Table 8-24

PARAMETER: Wavelength

MATERIAL: Silver

FORM Film

THICKNESS $0.75 \times 10^{-6}$ to bulk mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Misc.

REFERENCE Mayer [1950]

REMARKS Compilation of older data

| Film Thickness, Å | Refractive Index, n @ Microns Wavelength | | | Observer |
|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | |
| 7.5 | 2.5 | 2.2 | | Murmann [1936] |
| 10 | 2.95 | 3.05 | | Krautkraemer [1938] |
| 15 | 2.3 | 2.6 | | Murmann [1936] |
| 20 | 0.6 | 1.0 | | Murmann [1936] |
| ∞ | 0.20 | 0.23 | 0.26 | Kretzmann [1940] |

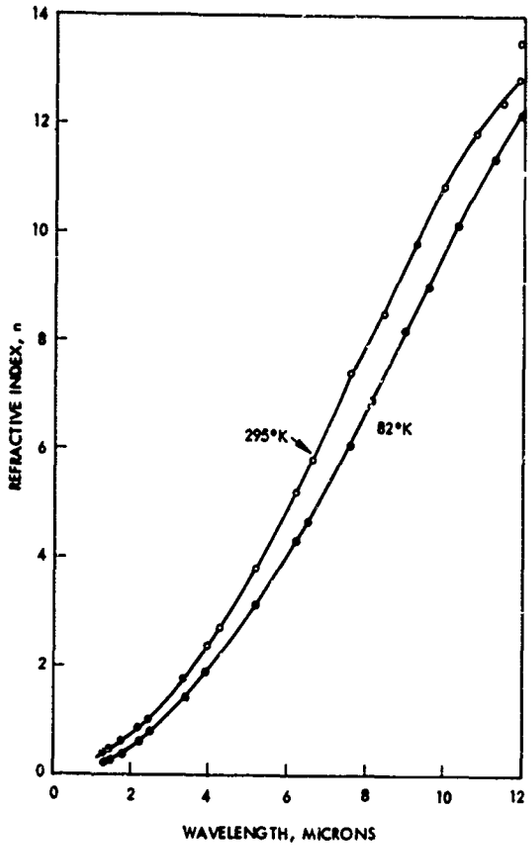
Table 8-25

| Film Thickness, Å | Extinction Coefficient, k @ Microns Wavelength | | | | Observer |
|---|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | 1.5 | |
| 7.5 | 5.15 | 5.2 | | | Murmann [1936] |
| 10 | 4.9 | 5.0 | | | Murmann [1936] |
| 15 | 5.1 | 5.35 | | | Murmann [1936] |
| 20 | 5.5 | 5.8 | | | Murmann [1936] |
| 500 | 6.21 | | 8.00 | 12.4 | Hagen & Rubens [1902] |
| ∞ | 5.54 | 6.25 | 6.93 | | Kretzmann [1940] |

Table 8-26

PARAMETER: Wavelength

MATERIAL: Silver




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 12 μ

TEMPERATURE 82, 295 °K

METHOD Reflection

REFERENCE Padalka & Shklyarevskii (9953)

REMARKS Evaporation from tantalum crucible onto glass substrate at $10^{-5}$ torr

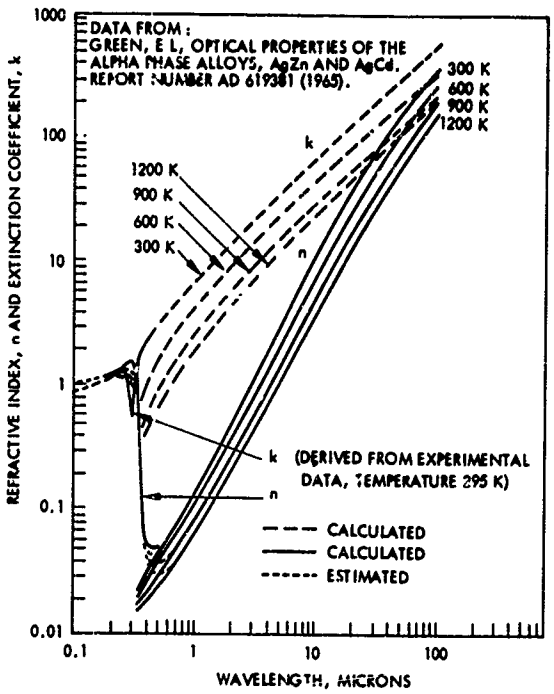
Figure 8-11

| Wavelength, (Microns) | Refractive Index, n | |
|---|---|---|
| | T = 295°K | T = 82°K |
| 1 | 0.25 | 0.22 |
| 2 | 0.68 | 0.57 |
| 3 | 1.38 | 1.14 |
| 4 | 2.34 | 1.92 |
| 5 | 3.52 | 2.88 |
| 6 | 4.87 | 4.02 |
| 7 | 6.31 | 5.31 |
| 8 | 7.86 | 6.70 |
| 9 | 9.36 | 8.10 |
| 10 | 10.8 | 9.60 |
| 11 | 12.0 | 10.9 |
| 12 | 12.8 | -- |

Table 8-27

PARAMETER: Wavelength

MATERIAL: Silver




FORM Not stated

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.3 - 100 μ

TEMPERATURE 300 - 1200 °K

METHOD NA

REFERENCE Grenis (30490)

REMARKS Calculated results, based on optical, conductivity and dielectric measurements.

Figure 8-12

| Wavelength, (Microns) | Refractive Index, n | Extinction Coefficient, k |
|---|---|---|
| 1.03 | 0.27 | 7.00 |
| 1.28 | 0.36 | 8.58 |
| 1.71 | 0.53 | 11.7 |
| 2.50 | 0.91 | 17.2 |
| 3.48 | 1.65 | 23.75 |
| 4.38 | 2.0 | 29.65 |
| 5.38 | 2.9 | 36.9 |
| 6.00 | 4.3 | 40.65 |

THICKNESS Not stated-Mirror mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 6 μ

TEMPERATURE ~298 °K

METHOD Reflection

REFERENCE Motulevich (40051)

REMARKS n-type, carrier concentration = $5.2 \times 10^2$ $cm^{-3}$

Table 8-28

PARAMETER: Film Thickness

MATERIAL: Silver

FORM Film

THICKNESS $0.75 \times 10^{-6}$ to bulk mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 0.8 - 1.0 μ

TEMPERATURE ~298 °K

METHOD Misc.

REFERENCE Mayer [1950]

REMARKS Compilation of older data

| Film Thickness, Å | Refractive Index, n @ Microns Wavelength | | | Observer |
|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | |
| 7.5 | 2.5 | 2.2 | | Murmann [1936] |
| 10 | 2.95 | 3.05 | | Krautkraemer [1938] |
| 15 | 2.3 | 2.6 | | Murmann [1936] |
| 20 | 0.6 | 1.0 | | Murmann [1936] |
| ∞ | 0.20 | 0.23 | 0.26 | Kretzmann [1940] |

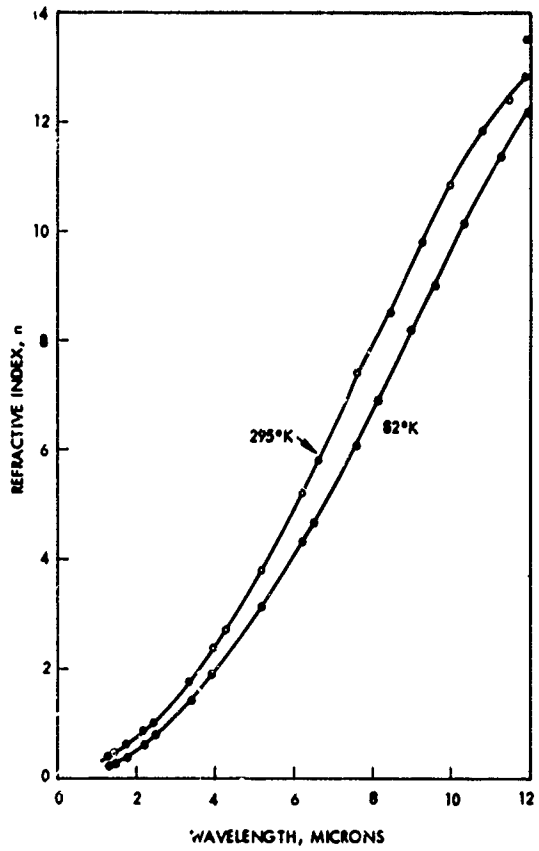
Table 8-29

| Film Thickness, Å | Extinction Coefficient, k @ Microns Wavelength | | | | Observer |
|---|---|---|---|---|---|
| | 0.8 | 0.9 | 1.0 | 1.5 | |
| 7.5 | 5.15 | 5.2 | | | Murmann [1936] |
| 10 | 4.9 | 5.0 | | | Murmann [1936] |
| 15 | 5.1 | 5.35 | | | Murmann [1936] |
| 20 | 5.5 | 5.8 | | | Murmann [1936] |
| 500 | 6.21 | | 8.00 | 12.4 | Hagen & Rubens [1902] |
| ∞ | 5.54 | 6.25 | 6.93 | | Kretzmann [1940] |

Table 8-30

PARAMETER: Temperature

MATERIAL: Silver




FORM Film

THICKNESS Not stated mm

RAY ORDINARY ☒, EXTRAORDINARY ☐

WAVELENGTH 1 - 12 μ

TEMPERATURE 82, 295 °K

METHOD Reflection

REFERENCE Padalka & Shklyarevskii (9953)

REMARKS Evaporation from tantalum crucible onto glass substrate at $10^{-5}$ torr

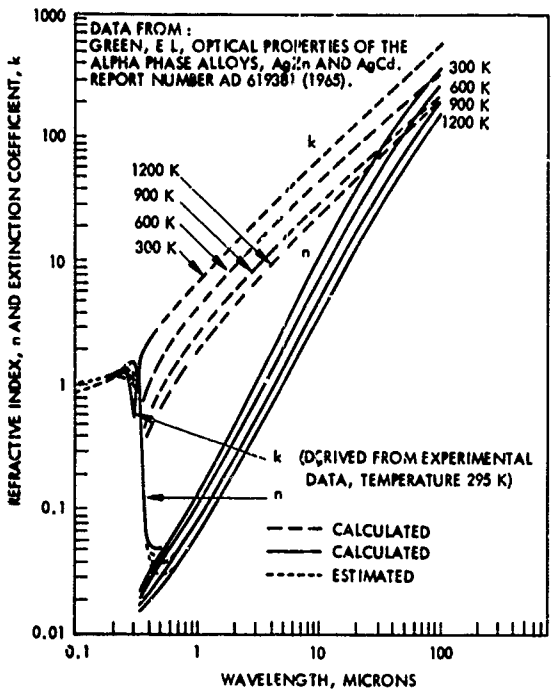
Figure 8-13

| Wavelength, Micron | Refractive Index, n | |
|---|---|---|
| | T = 295°K | T = 82°K |
| 1 | 0.25 | 0.22 |
| 2 | 0.68 | 0.57 |
| 3 | 1.38 | 1.14 |
| 4 | 2.34 | 1.92 |
| 5 | 3.52 | 2.88 |
| 6 | 4.87 | 4.02 |
| 7 | 6.31 | 5.31 |
| 8 | 7.86 | 6.70 |
| 9 | 9.36 | 8.10 |
| 10 | 10.8 | 9.60 |
| 11 | 12.0 | 10.0 |
| 12 | 12.8 | -- |

Table 8-31

**PARAMETER:** Temperature

**MATERIAL:** Silver




**FORM** Not Stated mm

**THICKNESS** Not Stated mm

**RAY** ORDINARY ☒, EXTRAORDINARY ☐

**WAVELENGTH** 0.3 - 100 μ

**TEMPERATURE** 300 - 1200 °K

**METHOD** NA

**REFERENCE** Grenis (30490)

**REMARKS** Calculated results, based on optical, conductivity and dielectric measurements.

Figure 8-14

## CHAPTER 9

## BIBLIOGRAPHY

### EPIC-INDEXED REFERENCES


ARONSON, J.R., et al., (16091) Low-Temperature Far-Infrared Spectra of Germanium and Silicon. PHYS. REV., v. 135, no. 3A, Aug. 3, 1964. p. A785-A788.

BALKANSKI, M. and J.M. BESSON, (22653). ECOLE NORMALE SUPERIEURE. FRANCE. Optical Properties of Degenerate Silicon. TN no. 2. Contract no. AF 61-052-789. 1965. DDC AD-619 581.

BALLARD, S.S, (12539). MICHIGAN UNIV. WILLOW RUN LAB. Optical Materials for Infrared Instrumentation. State-of-the-Art Rept., Rept. no. 2389-11-S, Jan. 1959. Contract no. Nonr 1224-12. ASTIA AD-217 367.

BIENIEWSKI, T.M. and S.J. CZYZAK, (8761). Refractive Indexes of Signal Hexagonal Zinc Sulfide and Cadmium Sulfide Crystals. OPTICAL SOC. OF AMERICA, J., v. 53, no. 4, Apr. 1963. p. 496-497.

BERMAN, L.V. and A.G. ZHUKOV, (36032). Optical Constants of Crystalline Quartz in the Far Infrared Region. OPT. AND SPECTRO., v. 21, no. 6, Dec. 1965. p. 401-404.

BRIXNER, B., (29206). Refractive-Index Interpolation for Fused Silica. OPTICAL SOC. OF AMERICA, J., v. 57, no. 5, May 1967. p. 674-676.

BURGIEL, J.C. et al., (34617). Refractive Indices of Zinc Oxide, Zinc Sulfide, and Several Thin-Film Insulators. ELECTROCHEM. SOC., J., v. 115, no. 7, July 1968. p. 729-732.

CARDONA, M. et al., (620). Dielectric Constant of Germanium and Silicon as a Function of Volume. PHYS. AND CHEM. OF SOLIDS, v. 8, Jan. 1959. p. 204-206.

CARDONA, M., (2569). HARVARD UNIV., GORDON McKAY LAB. OF APPL. SCI. Dielectric Constant of Germanium and Silicon as a Function of Volume. TR no. HP-5. Contract Nonr-186610. July 1, 1959. AD 226 982.

CHAMBERLAIN, J.E. and H.A. GEBBIE, (40177). Determination of the Refractive Index of a Solid Using a Far Infra-Red Maser. NATURE, v. 206, no. 4984, May 8, 1965. p. 602-603.

CHAMBERLAIN, J.E., et al., (40179). Refractometry in the Far Infra-Red Using a Two-Beam Interferometer. NATURE, v. 198, no. 4883, June 1, 1963. p. 874-875.

CLEEK, G.W., (27331). The Optical Constants of Some Oxide Glasses in the Strong Absorption Region. APPLIED OPTICS, v. 5, no. 5, May 1966. p. 771-776.

COLLINS, R.J., (40273). PURDUE UNIVERSITY. Infrared Properties of Germanium. Doctoral Thesis, Aug. 1953. p. 76-79.

BLOCK, W., et al, (36747). Material Measurement Schemes for the Far Infrared. APPLIED OPTICS, v. 7, no. 11, Nov. 1968. p. 2319-2320.

BOGENS, R.K. and A.G. ZHUKOV, (35268). The Optical Constants of Fused Quartz in the Far Infrared. J. OF APPLIED SPECTROSCOPY, v. 4, no. 1, Jan. 1966. p. 54-55.

BOND, W.L., (19989). Measurement of the Refractive Indices of Several Crystals. J. OF APPLIED PHYS., v. 36, no. 5, May 1965. p. 1674-1677.

BOSOMWORTH, D.R., (29681). Far-Infrared Optical Properties of Calcium Fluoride, Strontium Fluoride Barium Fluoride, and Cadmium Fluoride. PHYS. REV., v. 157, no. 3, May 15, 1967. p. 709-715.

BRATTAIN, W.H. and H.B. BRIGGS, (18391). The Optical Constants of Germanium in the Infra-Red and Visible. PHYS. REV., v. 75, no. 11, June 1, 1949. p. 1705-1710.

BRIGGS, H.B., (13314). Optical Effects in Bulk Silicon and Germanium. PHYS. REV., v. 77, no. 2, Jan. 15, 1950. p. 287.

COX, J.T., et. al., (17066). Improved Dielectric Films for Multilayer Coatings and Mirror Protection. J. DE PHYS., v. 25, no. 1-2, Jan.-Feb. 1964. p. 250-254.

CZYZAK, S.J., et. al., (6331). Refractive Indexes of Single Synthetic Zinc Sulfide and Cadmium Sulfide Crystals. OPTICAL SOC. OF AMERICA, J., v. 47, no. 3, Mar. 1957. p. 240-243.

CZYZAK, S.J., et al., (14914). DETROIT UNIV. The Study of Properties of Single Cadmium Sulfide and Zinc Sulfide Crystals for use as Detectors in Crystal Counters. TR no. 3. Contract no. Nonr 1511-01-NR-015-218. Oct. 1957. ASTIA AD-143 919.

DAVEY, J.E., et al., (13363). The Effect of Vacuum-Evaporation Parameters on the Structural, Electrical and Optical Properties of Thin Germanium Films. SOLID STATE ELECTRONICS, v. 6, no. 3, May-June 1964. p. 205-216.

DAVIS, P.W. and T.S. SHILLIDAY, (3648). Some Optical Properties of Cadmium Telluride. PHYS. REV., v. 118, no. 4, May 15, 1960. p. 1020-1022.

DE NOBEL, D., (306). Phase Equilibria and Semiconducting Properties of Cadmium Telluride. PHILIPS RES. REP., v. 14, no. 4, Aug. 1959. p. 361-399.

DEVORE, J.R., (40276). Refractive Indices of Rutile and Sphalerite. OPTICAL SOC. OF AMERICA, J., v. 41, no. 6, June 1951. p. 416-419.

DIANOV, E.M. and N.A. IRISOVA, (41423). Determination of the Absorption Coefficient of Solids in the Short-Wave Region of the Millimeter Band. J. OF APPLIED PHYS., v. 5, no. 2, Aug. 1966. p. 187-189.

DOLD, B.B. and R. MECKE, (27079). Optische Eigenschaften von Edelmetallen, Uebergangsmetallen und deren Legierungen im Infrarot. 1 Teil. Optical Properties of Precious Metals, Transition Metals and their Alloys in the Infrared. Part I. OPTIK, v. 22, no. 6, 1965. p. 435-446.

EVANS, R.A., (26567). RESEARCH TRIANGLE INST., DURHAM, N.C. Physical/Electrical Properties of Silicon. ASD-TDR-63-316. Contract AF 33(657)10340. July 1964. p. 177. AD 605 558.

FISCHER, A.G., et al., (15559). RCA LABS. DAVID SARNOFF RES. LABS. Investigation of Carrier Injection Electrol minescence. Semiannual SR no. 2, for Jan. 15-July 15, 1962. AFCRL-62-588. Contract no. AF 19-604-8018. Aug. 15, 1962. ASTIA AD-290 231.

FISHER, P. and H.Y. FAN, (5400). Infrared Properties and Effective Ionic Charge of Cadmium Telluride. AMERICAN PHYS. SOC., BULL., v. 4, 1959. p. 409.

GARLICK, G.F.J., et al., (7771). The Nature of Binding in Cadmium Telluride. PHYS. SOC., PROC., v. 72, pt. 5, Nov. 1958. p. 925-926.

GEICK, R., (39706). Refractive Index of Crystalline and Fused Quartz at 100 Microns (In Ger.). Z. FUER PHYS., v. 161, Jan. 1961. p. 116-122.

GISIN, M.A. and V.A. IVANOV, (41222). Optical Properties of Thin Germanium Films in the Infrared Region of the Spectrum. OPT. AND SPECTRO., v. 26, no. 2, Feb. 1969. p. 124-125.

GOLOVASHKIN, A.I., et al., (14298). Determination of Microscopic Parameters of Aluminum from Its Optical Constants and Electric Conductivity. SOVIET PHYS. - JETP, v. 11, no. 1, July 1960. p. 38-41.

GRENIS, A.F., (30490). ARMY MATERIALS RES. AGENCY, WATERTOWN, MASS. The Interrelation of the Thermophysical Properties of Silver. TR. AMRA TR 67-02. Jan. 1967. 14 p. AD 649 515.

GRIGOROVICI, R. and A. VANCU, (35455). Optical Constants of Amorphous Silicon Films Near the Main Absorption Edge. THIN SOLID FILMS, v. 2, no. 1-2, July 1968. p. 105-110.

GRYVNAK, D.A. and D.E. BURCH, (21068). Optical and Infrared Properties of Aluminum Oxide at Elevated Temperatures. OPTICAL SOC. OF AMERICA, J., v. 55, no. 6, June 1965. p. 625-629.

HADNI, A., et al., (34136). Absorption and Reflection Spectra in the Far Infrared of Zinc Selenide, Zinc Telluride and Cadmium Selenide at Low Temperatures (In Fr.). PHYS. STATUS SOLIDI, v. 26, no. 1, Mar. 1, 1968. p. 241-252.

HADNI, A., et al., (29510). Constantes Optiques de Sept Cristaux Ioniques A Basse Temperature Dans le Infrarouge Lointain, Processus de Difference, Role des Impurities. Optical Constants of Seven Ionic Crystals at Low Temperatures in the Infrared Region, Energy Levels, Role of Impurities. J. DE PHYSIQUE, v. 28, no. 2, Feb. 1967. p. C1-118 - C1-128.

HAEFELE, H.G., (9762). Das infrarotspektrum des rubins. Infrared Spectrum of Ruby. ZEITSCHRIFT FUER NATURFORSCHUNG, vol. 18a, no. 3, March 1963. p. 331-335.

HAEFELE, H.G., (34826). Optical Constants of Magnesium Oxide in the Infrared (In Ger.). ANNALEN DER PHYSIK, v. 10, no. 5-6, 1963. p. 321-326.

HAEFELE, H.G., et al., (40240). The Optical Constants of Quartz in the Infrared and their Temperature Dependence I. (In Ger.). Z. FUER PHYS., v. 168, no. 5, July 1962. p. 530-541.

HALL, J.F., Jr. and W.F.C. FERGUSON. (2609). Optical Properties of Cadmium Sulfide and Zinc Sulfide from 0.6 Micron to 14 Microns. OPTICAL SOC. OF AMERICA, J., v. 45, no. 9 Sept. 1955. p. 714-718.

HALL, J.F., Jr., (13466). Optical Properties of a Highly Boron-Doped Silicon Surface. OPTICAL SOC. OF AMERICA, J., v. 50, no. 7, July 1960. p. 717-720.

HALSTED, R.E., et al., (26678). GEN. ELECTRIC CO., SCHENECTADY, N.Y. RES. LAB. Research on Cadmium Telluride. Contract No. AF 33 616-8264. Oct. 1965. 39 p. AD 626 941.

HARRIS, L., (17011). Preparation and Infrared Properties of Aluminum Oxide Films. OPTICAL SOC. OF AMERICA, J., v. 45. no. 1, Jan. 1955. p. 27-29.

HARRIS, L. and J. PIPER, (5212). Transmittance and Reflectance of Aluminum-Oxide Films in the Far Infrared. OPTICAL SOC. OF AMERICA, J., v. 52, no. 2, Feb. 1962. p. 223-224.

HEILMANN, G., (40178). The Extinction Coefficient and Refractive Index of Calcium Fluoride in the Infrared Region (In Ger.). Z. FUER PHYS., v. 176, no. 3, 1963. p. 253-260.

HILTON, A.R., et al., (25628). TEXAS INSTRUMENTS INC. New High Temperature Infrared Transmitting Glasses. Semiannual Tech. Summary Rept. no. 2, May 1-Oct. 31, 1963. TI Rept. no. 08-63-167. Contract no. 3810 00. Oct. 31, 1963. N64-12336.

HULDT, L. and T. STAFLIN, (3735). Optical Constants of Evaporated Films of Zinc Sulphide and Germanium in the Infra-red. OPTICA ACTA, v. 6, no. 1, Jan. 1959. p. 27-36.

IRVIN, J.C., (5250). Resistivity of Bulk Silicon and of Diffused Layers in Silicon. BELL SYSTEM TECH. J., v. 41, no. 2, Mar. 1962. p. 387-410.

JACOBSSON, R., (40180). Optical Properties in the Near Infrared of Thin Germanium-Zinc Sulfide Films Produced by Simultaneous Evaporation from Two Sources. ARKIV FOER FYSIK, v. 24, no. 2, 1962. p. 17-30.

JASPERSE, J.R., et al., (34832). Temperature Dependences of Infrared Dispersion in Ionic Crystals Lithium Fluoride and Magnesium Oxide. PHYS. REV., v. 146, no. 2, June 10, 1966. p. 526-542.

JENNES, J.R., Jr., (40476). Reflection-Reducing Coatings of Magnesium Fluoride and Lithium Fluoride in the Near Infrared. OPTICAL SOC. OF AMERICA, J., v. 46, no. 3, Mar. 1956. p. 157-159.

JOHNSON, C.J., et al., (40781). Far Infrared Measurement of the Dielectric Properties of Gallium Arsenide and Cadmium Telluride at 300°K and 8°K. APPLIED OPTICS, v. 8, no. 8, Aug. 1969. p. 1667-1671.

KAISER, W., et al. (40176). Infrared Properties of Calcium Fluoride, Strontium Fluoride, and Barium Fluoride. PHYS. REV., v. 127, no. 6, Sept. 15, 1962. p. 1950-1954.

KONAK, C., (11590). Einige optische Eigenschaften von Kadmium-Tellurid. Some Optical Properties of Cadmium Telluride. PHYSICA STATUS SOLIDI, vol. 3, no. 7, 1963. p. 1274-1278.

KORNFELD, M.I., (14254). Dispersion of Light in Germanium. SOVIET PHYS. - SOLID STATE, v. 2, no. 1, July 1960. p. 42-43.

KRETZMANN, R., (40353). Optical Constants of Thick Metal Films in the Visible and Near Infrared. ANNALEN DER PHYSIK, v. 37, Ser. 5, 1940. p. 303-325.

KUWABARA, G. and K. ISIGURO, (40442). Optical Constants of Zinc Sulfide Films. PHYS. SOC. OF JAPAN, J., v. 7, no. 1, Jan.-Feb. 1952. p. 72-74.

LADD, L.R.S., (27063). Cadmium Telluride Infrared Transmitting Material. INFRARED PHYS., v. 6, 1966. p. 145-151.

LOEWENSTEIN, E.V., (17012). Optical Properties of Sapphire in the Far Infrared. OPTICAL SOC. OF AMERICA, J., v. 51, no. 1, Jan. 1961. p. 108-112.

LORIMOR, O.G. and W.G. SPITZER, (20784). Infrared Refractive Index and Absorption of Indium Arsenide and Cadmium Telluride. J. OF APPLIED PHYS., v. 36, no. 6, June 1965. p. 1841-1844.

LUKES, F., (3924). Optical Constants of Thin Germanium Films. CZECH. J. OF PHYS., v. 10, no. 1, 1960. p. 59-65.

LUKES, F., (3914). The Temperature Dependence of the Refractive Index of Germanium. CZECH. J. OF PHYS., v. 8, no. 2, 1958. p. 253-254.

LUKES, F., (3915). The Temperature Dependence of the Refractive Index of Germanium. CZECH. J. OF PHYS., v. 10, no. 10, 1960. p. 742-748.

LUKES, F., (3382). The Temperature-Dependence of the Refractive Index of Silicon. PHYS. AND CHEM. OF SOLIDS, v. 11, no. 3-4, Oct. 1959. p. 342-344.

LUKES, F., (4541). The Temperature Dependence of the Silicon Refractive Index (In. Ger.). CZECH. J. OF PHYS., v. 10, no. 4, 1960. p. 317-326.

McCARTHY, D.E., (26010). The Reflection and Transmission of Infrared Materials. III. Spectra from 2 Microns to 50 Microns. APPLIED OPTICS, v. 4, no. 3, 1965. p. 317-320.

MALITSON, I.H., (21758). Interspecimen Comparison of the Refractive Index of Fused Silica. OPTICAL SOC. OF AMERICA, J., v. 55, no. 10, Oct. 1965. p. 1205-1209.

MALITSON, I.H., (39194). A Redetermination of Some Optical Properties of Calcium Fluoride. APPLIED OPTICS, v. 2, no. 11, Nov. 1963. p. 1103-1107.

MALITSON, I.H., (17008). Refraction and Dispersion of Synthetic Sapphire. OPTICAL SOC. OF AMERICA, J., v. 52, no. 12, Dec. 1962. p. 1377-1379.

MANABE, A., et al., (36435). OSAKA UNIV. Far Infrared Optical Properties of Cadmium Telluride. TECHNOL. REPTS., v. 17, Oct. 1967. p. 263-275.

MANABE, A., et al., (28526). Infrared Lattice Reflection Spectra of II-VI Compounds. JAPAN. J. OF APPL. PHYS., v. 6, no. 5, May 1967. p. 593-600.

MARPLE, D.T.F., (10559). Effective Electron Mass in Cadmium Telluride. PHYSICAL REVIEW, vol. 129, no. 6, March 15, 1963. p. 2466-2470.

MARPLE, D.T.F., (15085). Refractive Index of Zinc Selenide, Zinc Telluride and Cadmium Telluride. J. OF APPLIED PHYS., v. 35, no. 3, Pt. 1, Mar. 1964. p. 539-542.

MILER, M., (34239). Infrared Absorption of Glassy Silicon Dioxide. CZECH. J. OF PHYS., v. 18B, no. 3, 1968. p. 354-362.

MILLER, M., (21593). Infrared Dispersion Due to Network Vibrations in Fused Silica. PHYS. STATUS SOLIDI, v. 10, no. 2, Aug. 1965. p. K119-K121.

MITSUISHI, A., (481). The Optical Properties of Cadmium Telluride in the Far Infrared Region. PHYS. SOC. OF JAPAN, J., v. 16, no. 3, Mar. 1961. p. 533-537.

MOMULEVICH, G.P. and A.A. SHUBIN, (40051). Determination of the Optical Constants of Metals in the Infrared Range. OPTIKA I SPEKTROSKOPIYA, v. 2, no. 5, May 1957. p. 634-636.

MOTULEVICH, G.P., et al., (25734). The Effect of Periodic Structure on the Optical Properties of Aluminum. SOVIET PHYS. - JETP, v. 22, no. 5, May 1966. p. 984-985.

MOTULEVICH, G.P. and A.A. SHUBIN, (19922). Influence of Fermi Surface Shape in Gold on the Optical Constants and Hall Effect. SOVIET PHYS. - JETP., v. 20, no. 3, Mar. 1965. p. 560-564.

NEU, J.T., et al., (40360). GENERAL DYNAMICS CORP. SAN DIEGO, CALIF. Evaluation of the Effects of Space Environment Exposure on Index of Refraction and Extinction Coefficients of Apollo Window Materials, NASA CR-1019. Apr. 1968. p. 105.

NEUROTH, N., (40354). Determination of the Refractive Index and Absorption Coefficient from Reflection Measurements. Z. FUER PHYS., v. 144, no. 1-3, 1956. p. 85-90.

NORTON CO. REFRACTORIES DIV., (16227). Properties and Literature References on Magnorite Fused Magnesium Oxide. Rept. no. P-1.5-1. Mar. 1, 1962.

OSWALD, R. and R. SCHADE, (2139). Ueber die Bestimmung der optischen Konstanten von Halbleitern des Typus Trivalent A-Pentavalent B im Infraroten. On the Determination of the Optical Constants of Semiconductors of Type Trivalent A-Pentavalent B in the Infrared. ZEITSCHRIFT FUER NATURFORSCHUNG, v. 9a, no. 7/8, July-Aug. 1954. p. 611-617.

PADALKA, V.G. and I.N. SHKLYAREVSKII, (9953). Determination of the Microcharacteristics of Silver and Gold From Infrared Optical Constants and the Conductivity at 82 and 295 Degrees K. OPTICS AND SPECTROSCOPY, vol. 11, no. 4, October 1961. p. 285-288.

PHILIPP, H.R. and E.A. TAFT, (7113). Optical Constants of Germanium in the Region 1 to 10 ev. PHYS. REV., v. 113, no. 4, Feb. 15, 1959. p. 1002-1005.

PHILIPP, H.R. and E.A. TAFT, (5951). Optical Constants of Silicon in the Region 1 to 10 eV. PHYS. REV., v. 120, no. 1, Oct. 1960. p. 37-38.

PIPER, W.W., et al., (735). Optical Properties of Hexagonal Zinc Sulfide Single Crystals. PHYS. REV., v. 110, no. 2, Apr. 15, 1958. p. 323-326.

PIRIOU, B., (29797). Etude Des Bandes de Rayons Restants de la Magnesie et du Corindon. Influence de la Temperature. Study of Residual Spectra in Magnesium Oxide and Aluminum Oxide. Temperature Influence. REV. HAUTES TEMP. REFRACTAIRES, v. 3, no. 1, Jan.-Mar. 1966. p. 109-114.

PLANKER, K.J. and E. KAUER, (40526). Determination of Effective Mass of Free Charge Carriers in Semi-Conductors from Infrared Absorption (In Ger.). Z. FUER ANGEWAND. PHYS., v. 12, no. 9, Sept. 1960. p. 425-432.

PLISKIN, W.A. and E.E. CONRAD, (36787). Nondestructive Determination of Thickness and Refractive Index of Transparent Films. IBM J. OF RES. AND DEVELOPMENT, v. 8, no. 1, Jan. 1964. p. 43-51.

POINSOT, P. et al., (40710). Lattice Spectrometer for the Infrared, Study of Barium Titanate, Quartz and Liquid Water (In Fr.). ACAD. DES SCI., C.R., v. 253, Ser. B, no. 19, Nov. 6, 1961. p. 2049-2051.

POTTER, R.F., (27255). Optical Constants of Germanium in Spectral Region from 0.5 eV to 3.0 eV. PHYS. REV., v. 150, no. 2, Oct. 14, 1966. p. 562-567.

RAMADIER-DELBES, J., (39712). Ordinary Index of Refraction of Quartz from 5 to 14 Microns (In Fr.). J. DE PHYSIQUE ET LE RADIUM, v. 12, no. 10, Dec. 1951. p. 954.

RANDALL, C.M. and R.D. RAWCLIFFE, (33290). Far Infrared Optical Properties of Pressed Cadmium Telluride. APPLIED OPTICS, v. 7, no. 1, Jan. 1968. p. 213.

RANDALL, C.M. and R.D. RAWCLIFFE, (33251). Refractive Indices of Germanium, Silicon, and Fused Quartz in the Far Infrared. APPLIED OPTICS, v. 6, no. 11, Nov. 1967. p. 1889-1895.

RANK, D.H., et al., (39713). The Index of Refraction of Germanium Measured by an Interference Method. OPTICAL SOC. OF AMERICA, J., v. 44, no. 1, Jan. 1954. p. 13-16.

ROBERTS, S. and D.D. COON, (18253). Far-Infrared Properties of Quartz and Sapphire. OPTICAL SOC. OF AMERICA, J., v. 52, no. 9, Sept. 1962. p. 1023-1029.

ROCHOW, E.G., (8766). The Unique Element Germanium. INDUSTRIAL AND ENG. CHEM., v. 55, no. 3, Mar. 1963. p. 32-35.

RODNEY, W.S. and R.J. SPINDLER, (39714). Index of Refraction of Fused-Quartz Glass for Ultraviolet, Visible, and Infrared Wavelengths. NAT. BUREAU OF STANDARDS, J. OF RES., v. 53, no. 3, Sept. 1964. p. 185-189.

ROWNTREE, R.F., (34819). OHIO STATE UNIV., COLUMBUS, RES. FOUNDATION. Measurements of the Optical Constants of Magnesium Oxide and Calcium Tungstate (Spectral Region Between 10 $CM^{-1}$ and 100 $CM^{-1}$ at 300°K and 90°K). Sci. Rept. No. 4, Contract No. AF 19 604-4119. Feb. 1963. AD 403 425. 154 p.

SIMON, I., (39827). Spectroscopy in Infrared by Reflection and Its Use for Highly Absorbing Substances. OPTICAL SOC. OF AMERICA, J., v. 41, no. 5, May 1951. p. 336-345.

SPITZER, W.G. and H.Y. FAN, (791). Determination of Optical Constants and Carrier Effective Mass of Semiconductors. PHYS. REV., v. 106, no. 5, June 1, 1957. p. 882-890.

SPITZER, W.G., et al., (13860). Effect of Heat Treatment on the Optical Properties of Heavily Doped Silicon and Germanium. J. OF APPLIED PHYS., v. 35, no. 1, Jan. 1964. p. 206-211.

SPITZER, W.G. and D.A. KLEINMAN, (18696). Infrared Lattice Bands of Quartz. PHYS. REV., v. 121, no. 5, Mar. 1, 1961. p. 1324-1335.

STEPHENS, R.E. and I.H. MALITSON, (34823). Index of Refraction of Magnesium Oxide. NBS J. OF RES., v. 49, no. 4, Oct. 1952. p. 249-252.

SZE. S.M. and J.C. IRVIN, (34530). Resistivity, Mobility and Impurity Levels in Gallium Arsenide, Germanium, and Silicon at 300°K. SOLID STATE ELECTRONICS, v. 11, no. 6, June 1968. p. 599-602.

TAUC, J., et al., (22818). Optical Properties of Non-Crystalline Semiconductors. In INT. CONF. ON PHYS. OF NON-CRYSTALLINE SOLIDS, PROC., Delft, July 1964. Ed. by PRINS, J.A. N.Y., Intersci. Pub., 1965. p. 606-615.

VITRIKHOVSKIY, N.I., et al., (31017). Dispersion of the Refractive Indices of Cadmium Sulfur Selenide and Cadmium Telluride Single Crystals in the Visible and Infrared Spectrum Ranges. UKRAINSKII FIZ. ZH., v. 12, no. 5, May, 1967. p. 796-799.

WALES, J. et al., (31497). Optical Properties of Germanium Films in the 1-5 Micron Range. THIN SOLID FILMS, v. 1, no. 2, Sept. 1967. p. 137-150.

WEIL, R. and C.J. JOHNSON, (41152). Temperature Coefficient of the Refractive Index and Optical Absorption of Cadmium Telluride at 10.6-Microns Wavelength. J. OF APPLIED PHYS., v. 40, no. 11, Oct. 1969. p. 4681-4682.

WEISS, K., (6107). Ueber optische Konstanten und elektrischen Widerstand dicker Metallschichten. The Optical Constants and the Electrical Resistivity of Thick Metal Layers. ZEITSCHRIFT FUER NATURFORSCHUNG, v. 3A, 1948. p. 143-147.

RUSSELL, E.E. and E.E. BELL, (28888). Measurement of the Optical Constants of Crystal Quartz in the Far Infrared with the Asymmetric Fourier-Transform Method. OPTICAL SOC. OF AMERICA, J., v. 57, no. 3, Mar. 1967. p. 341-348.

RUSSELL, E.E. and E.E. BELL, (28755). Optical Constants of Sapphire in the Far Infrared. OPTICAL SOC. OF AMERICA J., v. 57, no. 4, Apr. 1967. p. 543-544.

SALZBERG, C.D. and J.J. VILLA, (39254). Index of Refraction of Germanium. OPTICAL SOC. OF AMERICA, J., v. 48, no. 8, Aug. 1958. p. 579.

SALZBERG, C.D. and J.J. VILLA, (3900). Infrared Refractive Indexes of Silicon Germanium and Modified Selenium Glass. OPTICAL SOC. OF AMERICA, J., v. 47, no. 3, Mar. 1957. p. 244-246.

SATO, T., (29333). Spectral Emissivity of Silicon. JAPAN J. OF APPL. PHYS., v. 6, no. 3, Mar. 1967. p. 339-347.

SCHULZ, L.G., (27634). The Optical Constants of Silver, Gold, Copper, and Aluminum. I. The Absorption Coefficient k. OPTICAL SOC. OF AMERICA, J., v. 44, no. 5, May 1954. p. 357-361.

SCHULZ, L.G. and F.R. TANGHERLINI, (27635). Optical Constants of Silver, Gold, Copper, and Aluminum. II. The Index of Refraction. OPTICAL SOC. OF AMERICA, J., v. 44, no. 5, May 1965. p. 362-368.

SERAPHIN, B.O. and N. BOTTKA, (38093). Franz-Keldysh Effect of the Refractive Index in Semiconductors. PHYS. REV., v. 139, no. 2A, July 19, 1965. p. A560-A564.

SHKLIAREVSKII, I.N. and V.G. PADALKA, (36056). Measurements of the Optical Constants of Copper, Gold and Nickel in the Infrared Region of the Spectrum. OPT. AND SPECTRO., v. 6, no. 1, Jan. 1959. p. 45-48.

SHKLYAREVSKII, I.N. and R.G. YAROVAYA, (19998). Quantum Absorption in Aluminum and Indium. OPTICS AND SPECTROSCOPY, v. 16, no. 1, Jan. 1964. p. 45-48.

SHKLYAREVSKII, I.N. and R.G. YAROVAYA, (27261). Quantum Absorption of Light in Gold. OPT. AND SPECTRO., v. 21, no. 2, Aug. 1966. p. 115-118

SIMON, I., (4799). Optical Constants of Germanium, Silicon, and Pyrite in the Infrared. OPTICAL SOC. OF AMERICA, J., v. 41, no. 10, Oct. 1951. p. 730.

WILLMITT, J.C., (34804). The Infra-Red Spectrum of Magnesium Oxide. PHYS. SOC., PROC., v. 63A, pt. 4, Apr. 1950. p. 389-402.

WOLFE, W.L., et al., (26316). UNIV. OF MICHIGAN. INST. OF SCI. AND TECHNOL. INFRARED LAB. Optical Constants of Germanium. Contract Cwb 10533. March 1964. DDC AD 435 012. 37 p.

YAROVAYA, R.G. and I.N. SHKLYAREVSKII, (36165). Investigation of Quantum Absorption in Silver. OPT. AND SPECTRO., v. 18, no. 5, May 1965. p. 465-467.

ZERNICKE, F., Jr., (39697). Refractive Indices of Ammonium Dihydrogen Phosphate and Potassium Dihydrogen Phosphate between 2000 Angstroms and 1.5 Microns. OPTICAL SOC. OF AMERICA, J., v. 54, no. 10, Oct. 1964. p. 1215-1220.

OTHER REFERENCES

AVERY [1952]. AVERY, D. G., "Optical Constants by Reflection," PROC. PHYS. SOC. (London), Vol. B65, (1952), pp. 425-428.

BEATTIE [1955]. Beattie, J. R., "Optical Constants of Metals in the Infra-Red-Experimental Methods," PHIL. MAG., Vol. 46, No. 373, Feb. 1955, pp. 235-245.

CARTWRIGHT [1934]. CARTWRIGHT, C. H., "Transmission Measurements in the Region from 50 to 240 Microns," Z. PHYSIK, Vol. 90, (1934), pp. 480-488.

COURVOISIER [1963]. COURVOISIER, J. C., et al, "Evaporation-Condensation Method for Making Germanium Layers for Transistor Purposes," SOLID-STATE ELECTRONICS, Vol. 6, May-June 1963, pp. 265-270.

DAVEY [1961]. DAVEY, J. E., "Textural Properties of Germanium Films," J. APPL. PHYS., Vol. 32, No. 5, (1961), pp. 877-880.

GOOS [1937]. GOOS, F., Z. PHYS., Vol. 106, (1937), pp. 37, et seq., quoted from Mayer [1950].

HAGEN& RUBENS [1902]. HAGEN, E. and H. RUBENS, ANN. D. PHYS., Ser. 4, Vol. 8, (1902), pp. 60 et seq., quoted from Mayer [1950].

HARINGHHUIZEN ET AL. [1937]. HARINGHHUIZEN, P. J., D. A. WAS and A. M. KRUITHOF, PHYSICA, Vol. 4, (1937), pp. 209 et seq., quoted from Mayer [1950].

HARTING [1948]. HARTING, A., Sitzungsberichte der Deutschen Akademie der Wissenschaften zu Berlin. Mathematisch-naturwissenschaftliche Klasse, No. IV, (1948), reported by: Landolt-Boernstein, "Zahlenwerte und Funktionen aus Physik, Chemie, Astronomie, Geophysik und Technik," Vol. II, Part 8, Springer Verlag, Berlin, (1962).

HEILMANN [1961]. Heilmann, G., "The Optical Constants of Calcium Fluoride in the Infrared, "Z. Naturforsch. Vol. 16a, (1961), pp. 714-716.

HILTON & JONES [1967]. HILTON, A. R. and C. E. JONES, "The Thermal Change in the Nondispersive Infrared Index of Optical Materials," APPLIED OPTICS, V. 6, No. 9, September 1967, p. 1513-1517.

IDCZAK [1967]. IDCZAK, E., "Optical Properties of Ag-Cr and Cr-Ag Double Layers in 0.4 - 1 Micron Wave Length Range, in: Hahan, E., Ed. Proceedings of the Second Colloquium on Thin Films 1967, Vandenhoeck & Ruprecht in Goettingen, Goettingen, Germany, 1968, pp. 241-248.

KODAK [1967]. EASTMAN KODAK CO., "Irtran Infrared Optical Material Condensed Data Sheet," No. U-71, Feb. 1967.

KOHLRAUSCH 1943. KOHLRAUSCH, F., "Praktische Physik," Vol. II, B. G. Teubner, Leipzig, (1943).

KRAUTKRAEMER [1938]. Krautkraemer, J., ANN. d. PHYS., Ser. 5, Vol. 32, (1938), pp. 66 et seq., quoted from Mayer [1950].

KRETZMANN [1940]. Kretzmann, R., Ann. d. Phys., Ser. 5, Vol. 37, (1940), pp. 301-306, quoted from Mayer [1950].

LAUFER [1965]. LAUFER, J. S., "High Silica, Quartz, and Vitreous Silica," J. OPT, SOC. AM., Vol. 55, No. 4, April 1965, pp. 458-460.

MAYER [1950]. MAYER, H., "Physik Duenner Schichten," Part I, WISSENSCHAFTLICHE VERLAGSGESELLSCHAFT, Stuttgart, 1950.

MURMANN [1936]. MURMANN, H., Z. PHYS., Vol. 101, (1936), pp. 208 et seq., quoted from Mayer 1950.

POGANY [1916]. POGANY, B., ANN. D. PHYS., Ser. 4, Vol. 49, (1916), pp. 57 et seq., quoted from Mayer 1950.

SMAKULA [1952]. SMAKULA, A., "Physical Properties of Optical Crystals With Special Reference to Infrared," Report No. AD 206 298 (1952).

STATESCU [1910]. STATESCU, C., ANN. D. PHYS., Ser. 4, Vol. 33, (1910), pp. 27 et seq., quoted from Mayer [1950].

WOLFE [1965]. WOLFE, W. L., Ed., "Handbook of Military Infrared Technology," U. S. Government Printing Office, Washington, D.C., 1965.

Unclassified
Security Classification

## DOCUMENT CONTROL DATA - R & D

*(Security classification of title, body of abstract and indexing annotation must be entered when the overall report is classified)*

| | |
|---|---|
| 1. ORIGINATING ACTIVITY *(Corporate author)*<br>Hughes Aircraft Company<br>Culver City, California 90230 | 2a. REPORT SECURITY CLASSIFICATION<br>Unclassified<br>2b. GROUP |

3. REPORT TITLE

Refractive Index of Optical Materials in the Infrared Region

4. DESCRIPTIVE NOTES *(Type of report and inclusive dates)*
Data Sheet

5. AUTHOR(S) *(First name, middle initial, last name)*

A.J. Moses

| | | |
|---|---|---|
| 6. REPORT DATE<br>January 1970 | 7a. TOTAL NO. OF PAGES<br>246 | 7b. NO. OF REFS<br>154 |
| 8a. CONTRACT OR GRANT NO<br>F33615-68-C-1225<br>b. PROJECT NO<br>7381 and 8975<br>c. Task No. 738103 and 897503<br>d. | 9a. ORIGINATOR'S REPORT NUMBER(S)<br>DS-166<br>9b. OTHER REPORT NO(S) *(Any other numbers that may be assigned this report)* | |

10. DISTRIBUTION STATEMENT
This document has been approved for public release and sale; its distribution is unlimited.

| | |
|---|---|
| 11. SUPPLEMENTARY NOTES | 12. SPONSORING MILITARY ACTIVITY<br>Air Force Materials Laboratory<br>Air Force Systems Command<br>Wright-Patterson, AFB, Ohio 45433 |

13. ABSTRACT

Refractive index data and some extinction coefficients are provided for the infrared region for the following materials: silicon, germanium, zinc sulfide, cadmium telluride, zinc selenide, silica, calcium fluoride, magnesium fluoride, aluminum oxide, magnesium oxide, aluminum, gold and silver. The dependence of these optical constants on wavelength, temperature, crystal form, film preparation technique, radiation and other factors is included.

DD FORM 1 NOV 65 1473

Unclassified
Security Classification

Unclassified
Security Classification

| 14 KEY WORDS | LINK A ROLE | LINK A WT | LINK B ROLE | LINK B WT | LINK C ROLE | LINK C WT |
|---|---|---|---|---|---|---|
| Infrared Measurements | | | | | | |
| Refractive index | | | | | | |
| Extinction Coefficient | | | | | | |
| Transmittance | | | | | | |
| Silicon | | | | | | |
| Germanium | | | | | | |
| Zinc Sulfide | | | | | | |
| Cadmium Telluride | | | | | | |
| Zinc Selenide | | | | | | |
| Silica (Quartz) | | | | | | |
| Calcium Fluoride | | | | | | |
| Magnesium Fluoride | | | | | | |
| Aluminum Oxide (Sapphire) | | | | | | |
| Magnesium Oxide | | | | | | |
| Aluminum | | | | | | |
| Gold | | | | | | |
| Silver | | | | | | |

Unclassified
Security Classification